

Supplementary material to:

A comprehensive overview on directing groups applied in metal catalyzed C-H functionalization chemistry

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Introduction

This supporting material covers literature in the field of directing group assisted C-H functionalization published until 2015. Since the main manuscript covers only literature from 2015 onwards. The SI is mainly organized as tables which are first of all organized according to the type of directing group. Selected examples of each directing group are discussed in the accompanying text sections. In cases where it helps the general understanding of a transformation, additional schemes or figures are added, for example to explain an important mechanism. In the first column of the tables (besides the *Entry* column) the structure of the directing group is displayed. In the second column the type of transformations which have been reported with this directing group will be listed in alphabetical order (e.g. alkylation, arylation, nitration, trifluoromethylation, etc.). Here it has to be mentioned that sometimes different publications use different terms for the very same transformation. For the sake of simplicity, in this review each transformation has the same name in all entries. For example, the coupling of olefins with arenes to give alkylated arenes is either classified as alkylation or hydroarylation. It was decided to look at the reaction product and see what happened to the part of the molecule which carried the DG. Hence, in case the arene carried the DG, the reaction is always classified as alkylation reaction. In the third column the reaction/coupling partner is listed. For some transformations, numerous examples have been reported with a specific directing group. For example, the direct arylation of ketones in ortho position knows many examples in the literature. It was aimed at being comprehensive in the regard that all DGs and potential transformations with the DG are listed, however, reporting every single variant of a given transformation would have been beyond the scope. In such cases typically the first report and important further developments are listed in the tables. For example, if originally for arylation reactive aryl iodides were required, relevant further examples would make more readily available aryl chlorides accessible for the same transformation, just to give an example. It is clear that such a selection will always be biased and you might find that one or the other example should have been selected differently.

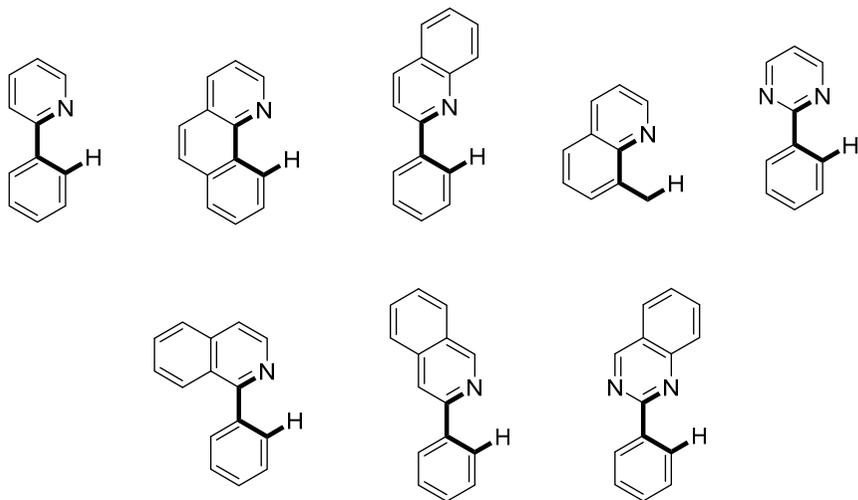
In the fourth column the structure of a typical product of the C-H activation reaction will be shown with the newly formed bond clearly indicated (bold or in color). In the fifth column general comments to the specific transformation are given. Most importantly which metal catalyst was required, was there a crucial additive (e.g. a specific base), or which solvent had to be applied. Additionally, information whether the directing group is cleavable or not is included here as well. Finally, in the sixth column the reference to the original research paper is given.

The format with a strong focus on tables and the aim to give a comprehensive overview on all DGs which have been applied in the past brings it about that not every contribution which is listed in a table can be discussed in the text. Discussions have been limited to examples of special interest, e.g. by establishing a new DG or a new catalytic system applicable to a manifold of other transformations. Such a selection made by the authors is naturally biased and not all readers will agree with the selections which have been made. However, once again it should be noted that the most important part are the tables and the information compiled therein.

The speed in which new contributions are brought forward in the field is amazing. This shows the high relevance of this area of research and the potential scientists see in it. For writers of a review it brings certain problems as well, most importantly when to make the cut for selecting contributions to be included. It was decided to include all original papers (full articles and communications) until the end of 2015.

Heterocyclic directing groups

The common feature of all the directing groups discussed in this section is that they contain a basic nitrogen which precoordinates the metal center. The most common representative in this area is without doubt pyridine. 2-Phenylpyridine is the single most applied starting material in C-H activation chemistry since it is very often used as test system to test a hypothesis for a viable new transformation and to optimize the required reactions conditions, before the method is then expanded to other directing groups. Hence, pyridine could make up for the largest chapter of this review and it could be expected that reviews on the direct functionalization of 2-phenylpyridine have been published in the past. However, this is not the case. Of course, 2-phenylpyridine finds its way into most of the C-H activation reviews in recent years, but not as prominent as the amount of work on this system would suggest. One reason is the limited synthetic potential of substituted 2-phenylpyridines. The DG cannot be cleaved from the arene system and hence, applying pyridine as DG in the framework of complex synthesis is limited to structures which actually do contain the 2-phenylpyridine motif. The same is true for a number of systems, which can be considered as close structural relatives of 2-phenylpyridine, and which are displayed in Scheme 1. It is not uncommon, that contributions dealing with 2-phenylpyridine activation also discuss some of the other examples of Scheme 1, and typically the same reaction conditions can be used without further optimization. All of these substrates have the same problem already mentioned, the permanent nature of the directing group, and hence their limited general applicability. Hence, these systems do not fit into the general goal of this review, as defined in the introduction, and it was decided to largely exclude them from coverage. Only selected examples will be reported, in case these examples fit the purpose of this review, to promote the application of C-H activation chemistry in complex synthesis. This is for example typically the case when conditions for cleaving the heterocyclic DG have been reported, which can be typically done when e.g. pyridine is not bound via a C-C bond to the system to be activated, but by a $C_{\text{pyridine}}\text{-Hetero}_{\text{Substrate}}$ bond.



Scheme 1: 2-Phenylpyridine and related substrates.

Reports dealing with heterocycle directed C-H activation are in most cases not only dedicated to a single heterocycle, but show the applicability of a method to several heterocycles. Most frequently, pyridine is first established as DG and the substrate scope of a given transformation is mainly shown with this DG. Then, the same set of reaction conditions is used to demonstrate also the applicability of other heterocycles, most frequently pyrimidine, but also pyrazole is an often used example. However, typically for these other heterocycles much less substrate scope explorations have been carried out. Still, cases of such contributions which are of special interest since for example a new heterocyclic DG is reported for the first time are included in this review, even if it might just be a single example.

Pyridine

As already mentioned, pyridine is the most frequently applied DG in C-H activation chemistry. However, only few examples have been reported in which the pyridine scaffold can be cleaved from the final products, or which show at least the potential for cleaving the DG. In these examples pyridine is typically attached to a heteroatom of the scaffold to be activated.

The group of Maes reported pyridine directed arylation of piperidine derivatives using the well-established $\text{Ru}_3(\text{CO})_{12}$ catalyst for this transformation (Table 1, Entry 18). Interestingly, they report a different mechanism than previously described for the same transformation by Sames, although promoted by a different DG (Table 1, Entry 16).¹ Mechanistically, the catalyst seems to be promiscuous, since in another study, the group of Schnürch showed that direct arylation of amines (this time acyclic ones) works under conditions which should favor the Meas mechanism (Table 1, Entries 33, 37-39), but also under conditions which would only allow the mechanism reported by Sames.² ³ The method of Maes leads to mixtures of mono- and bis-arylation in cases of simple piperidine, often as 1:1 mixtures (combined yields around 70%). If one α -position is blocked, naturally only mono-arylation occurred and 48-91% of products were obtained. In their paper, they also report a two-step protocol for cleaving the pyridine DG. Initially, it is reduced to a cyclic imine, which can then be hydrolyzed by the conditions reported by Sames previously.¹ In a later paper, they reported alternative cleavage protocols, namely hydrogenation-hydride reduction or quarternization-hydride reduction, adding to the small pool of pyridine removal conditions two more options.⁴ To overcome the problem of mixtures of mono- and bis-functionalization products being formed was addresses by the group of Schnürch by using a 3-trifluoromethylated pyridine DG (Table 1, Entry 38).⁵ Indeed, only mono-arylation was observed, which facilitated isolation of the products significantly. However, overall conversion remained low and only 60% yield in the best example was obtained. Cleavage of the modified DG required the removal of the CF_3 group since the reduction and hydrolysis protocol did not lead to any cleavage. Interestingly, after the reduction step, simple stirring the intermediate in DCM with silica gel led to quantitative removal of the CF_3 group, a thus far unprecedented reaction.

The group of Schnürch disclosed three different arylation protocols of a common type of substrate using different aryl sources (Table 1, Entries 33-35, 37-41).^{2, 3, 6, 7} Under $\text{Ru}(0)$ -catalysis and neutral conditions, arylboronic acid esters were used as coupling partners (Table 1, Entries 33, 37-39).^{2, 3} Expanding the method to aryl bromides and iodides required a $\text{Ru}(\text{II})$ catalyst and addition of base (Table 1, Entries 34 & 40).^{6, 7} The requirement for addition of KO Piv suggests that the reaction now proceeds via a

CMD mechanism. In contrast, when aryl chlorides are used as aryl source, KOPiv is not tolerated but a phosphine ligand (PPh₃) gives best results, still under Ru(II) catalysis and under basic conditions (Table 1, Entries 35 & 41).⁶ Additionally, the addition of a secondary alcohol is required, which acts as transfer hydrogenation agent, reducing an imine byproduct to the desired product.

Direct ortho-arylation of anilines with boronic acids as the aryl source was reported by Schnürch and coworkers (Table 1, Entry 49).⁸ Also in this case, the two-step reduction-hydrolysis protocol originally applied by Maes could be used for cleaving the pyridine DG from the aniline amino group. The reaction conditions required Ag₂O as oxidant and benzoquinone, which seems to act as oxidant as well, but also as an important ligand in the transformation.

Direct arylation of *N*-2-pyridyl carbazoles was reported by Wu and coworkers. Unsubstituted carbazoles (R^{1,2} = H) gave high yields of mono-arylation products. If one phenyl ring was already substituted, the nature and position of the substituent had a large effect on the outcome. A nitro group *meta* to the carbazole N led to exclusive arylation of the unsubstituted phenyl ring, whereas the same substituent in *para* position gave a mixture of two products. The electron donating methoxy group always led to mixtures of three products (mono-arylation of the MeO carrying ring + mono-arylation of the unsubstituted ring + bis-arylation). Other *meta* substituents (always relative to the carbazole N) such as *t*Bu and COMe only gave mono-arylation in the unsubstituted phenyl ring.

An interesting indole synthesis was reported by Wu and coworkers (Table 1, Entry 28).⁹ *N*-2-pyridyl anilines were reacted with alkynes using a simple system of Pd on CeO₂ under air giving an operationally quite simple protocol. In case of aryl-alkyl alkynes, the alkyl residue ended up in position 3 of the indole with good selectivity (7:1 or better). Alkynes bearing two different alkyl groups were not selective at all.

Cobalt catalyzed C-H activation has gained prominence in recent years. Ackermann and coworkers reported the direct arylation (Table 1, Entry 20) and benzylation (Table 1, Entry 22) of indoles at relatively mild conditions, however in a relatively rarely applied solvent, namely DMPU.¹⁰ The need for 2 equiv of a Grignard species limits naturally functional group tolerance.

A rare example of alkylation with an alkyl boron reagent was reported by the group of Li (Table 1, Entry 10).¹¹ Under Rh-catalysis, alkyl-BF₃K salts were efficiently reacted with indoles carrying pyridine as DG, amongst others. Especially interesting are the high yields in methylation reactions, since other alkylation protocols relying on alkenes as alkyl source do not give access to methylation products.

Cyanation in position 2 of indoles using *t*BuNC as the cyano source was reported by Xu and coworkers (Table 1, Entries 25 & 36).¹² The DG overrides the intrinsic reactivity of indoles, where the more electron rich 3-position would be preferentially cyanated in absence of a DG.

Oxidative coupling between indoles or pyrrole and *N*-oxides of quinoline, quinoxaline, and pyridine was reported by You and coworkers (Table 1, Entry 26).¹³ Such transformations are always attractive because no leaving group at all is required and basically two C-H bonds are used for the formation of a new C-C bond.

The group of Loh reported oxidative alkenylation (Table 1, Entry 2) and alkynylation (Table 1, Entry 12) under similar conditions using a simple and commercially available Rh catalyst.¹⁴ In both cases, the substrate scope regarding functional group tolerance was remarkable. As substrates indolines were used, and the new C-C bond formation took place in position 7. This is in contrast to indole, where similar methods lead to functionalization in C2 position. For both types of products, the cleavage of the DG was demonstrated as well.

A comprehensive study of [MnBr(CO)₅] catalyzed amidation of indoles with isocyanates was reported by the group of Ackermann (Table 1, Entry 14). Mn as catalyst is of course highly attractive and also the functional group tolerance was very good. Even such reactive groups as iodine were well tolerated. A small drawback are the temperature and pressure conditions required, since 100 °C in diethyl ether require special equipment not withstand the pressure built up in the reaction. The same group developed another non-precious metal catalyzed amidation method, this time using a Co catalyst, with 3-substituted 1,4,2-dioxazol-5-ones as amide source (Table 1, Entry 15).¹⁵ In this case, the newly formed bond is a C-N bond leading to regioisomeric amides as compared to the isocyanate method.

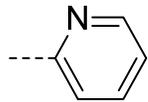
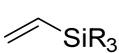
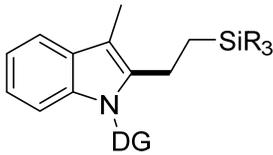
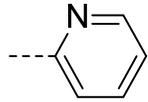
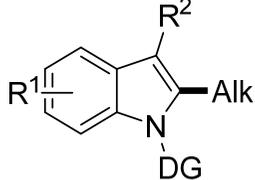
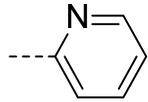
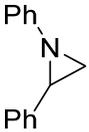
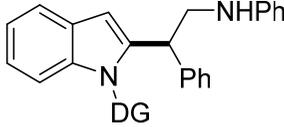
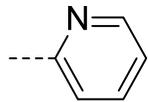
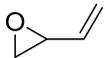
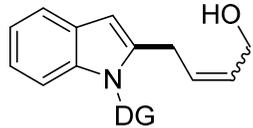
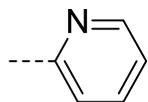
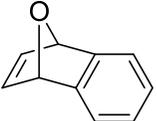
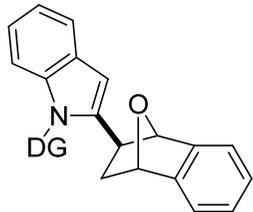
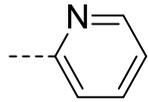
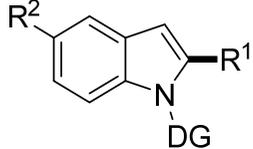
Also alkylation and arylation with alkyl chlorides (Table 1, Entry 6) and aryl chloride has been reported under Co-catalysis further demonstrating the potential of Co in C-H activation chemistry.¹⁶ The need for stoichiometric amounts of Grignard species is however a drawback regarding functional group tolerance.

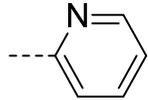
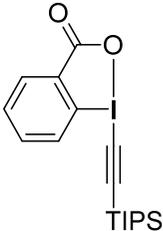
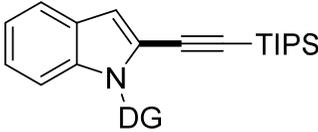
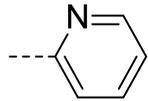
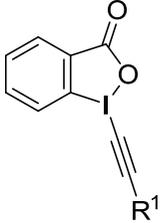
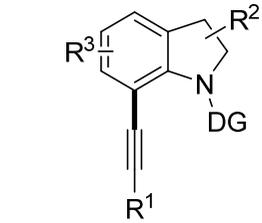
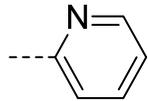
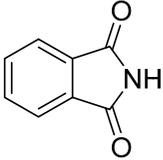
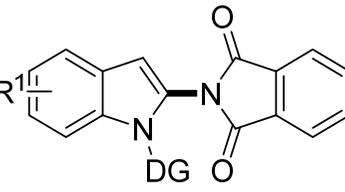
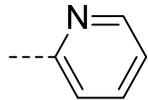
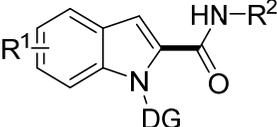
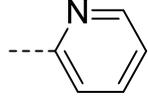
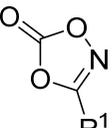
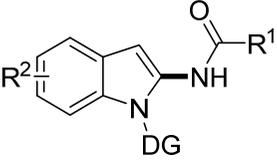
Palladium catalyzed alkenylation directed by 2-pyridylmethyl ether has been reported by You and Lan (Table 1, Entry 51).¹⁷ Coupling with acrylates, acrylamides or styrenes usually worked quite well. Due to the ether linker, the intermediate is a 7-membered palladacycle, usually less favored than 5- or 6-membered ones. Still, the yields obtained were generally good to excellent and the big advantage is the cleavability (via three different protocols as demonstrated!) of the DG leading to ortho-alkenylated phenols.

Alkylation of acyclic amines was reported initially by Jun, who showed that a methyl group in position 3 of the pyridine DG was crucial for good conversion (Table 1, Entry 32).¹⁸ Shibata and coworkers developed later an asymmetric version of this transformation under Ir-catalysis (Table 1, Entry 3).^{19, 20} Interestingly, the methyl group in position 3 was not required in this case. Remarkable *ees* for a C-H activation reaction were obtained, always >70% and in one case even 99% ee were reported.

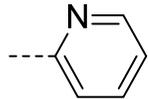
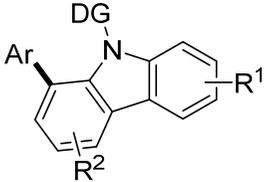
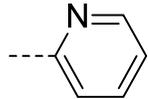
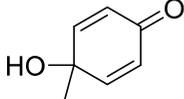
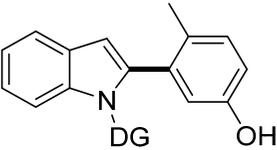
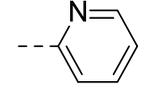
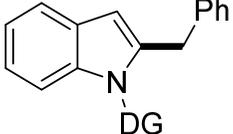
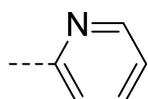
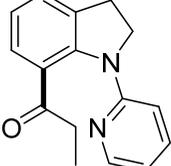
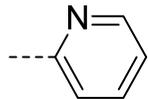
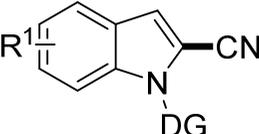
Table 1: Pyridine as directing group in C-H activation chemistry with the potential for directing group cleavage

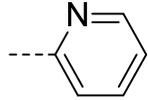
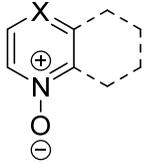
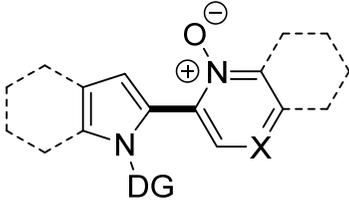
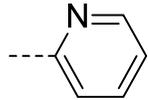
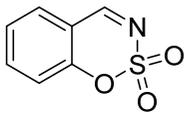
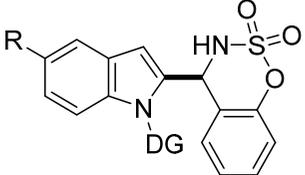
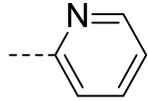
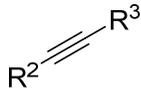
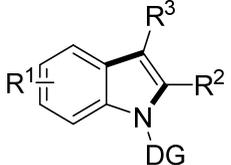
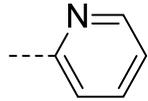
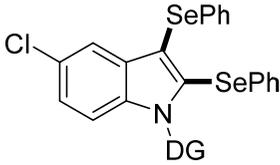
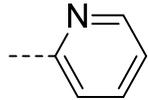
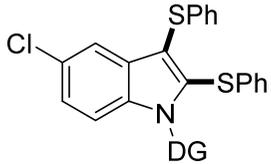
Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
1		Alkenylation			Substrate (1 equiv), alkyne (1.5 equiv), MnBr(CO) ₅ (10 mol%), DIPEA (20 mol%), PhCOOH (20 mol%), Et ₂ O, 80 °C, Ar, 12 h. single example, 81%	21
2		Alkenylation			Substrate (1 equiv), alkene (5 equiv), [Cp*RhCl ₂] ₂ (4.5-10 mol%), Cu(OAc) ₂ (2 equiv), DCE, 100 °C, 12-24 h. R ¹ = aryl, alkyl; R ² = H, Me, Ph; 27 examples, 34-94% In case the double bond can migrate this occurred and mixtures of E/Z isomers were obtained DG cleavage: 1) MeOTf, MeCN 2) NaBH ₄ , MeOH	14
3		Alkylation			Substrate (1 equiv), alkene (8 equiv), [Ir(cod) ₂][BF ₄] (10 mol%), (S)-tolBINAP (10 mol%), DME, 75-85 °C, 72 h; R ¹ = Me, Et, <i>n</i> Pr, <i>n</i> Pent; R ² = alkyl, aryl, Bn, CH=CHPh, COOR, SiR ₃ , CH ₂ SiR ₃ ; 18 examples, 33-87%; 72-99% <i>ee</i> ;	19, 20
4		Alkylation			Substrate (1 equiv), alkene (10 equiv), Ru ₃ (CO) ₁₂ (4 mol%), <i>trans</i> -Cy(COOH) ₂ (4 mol%), (<i>i</i> Pr) ₂ CHOH (5 equiv), 140 °C, 24 h. R ¹ = <i>n</i> Bu, <i>n</i> -nonyl; R ² = H, Ph, COOMe, OMe, -O(CH ₂) ₂ O-; Mixtures of mono and bis-alkylation products are formed. 26-48% mono-product; 43-76% bis-product.	22, 23

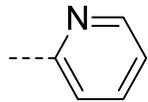
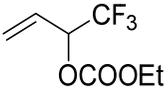
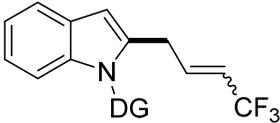
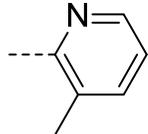
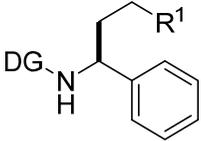
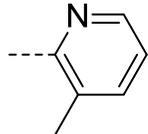
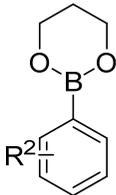
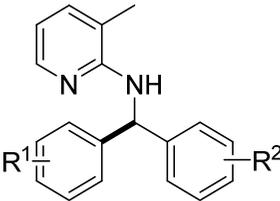
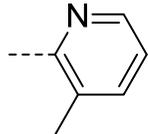
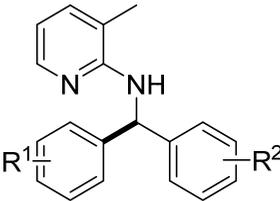
5		Alkylation			Substrate (1 equiv), alkene (3 equiv), [RuCl ₂ (p-cymene)] ₂ (2.5 - 5 mol%), MesCOOK (30 mol%), toluene, 100 - 120 °C, 18 - 24 h. 2 examples, R = Me (95%), Et (77%).	24
6		Alkylation	Alk-Cl		Substrate (1 equiv), Alk-Cl (1.2 equiv), Co(acac) ₂ (10 mol%), IPrHCl (20 mol%), CyMgCl, DMPU, 23 °C, 16 h. R ¹ = H, OMe; R ² = H, Me; Alk = <i>n</i> Hex, <i>n</i> Oct, (CH ₂) ₃ Ph; 4 examples, 67-97%.	16
7		Alkylation via aziridine opening			Substrate (1 equiv), aziridine (2 equiv), [Cp*RhCl ₂] ₂ (5 mol%), AgSbF ₆ (30 mol%), PhCl, 100 °C, 20 h. The reaction was developed for 2-arylpyridine derivatives (21 examples, 48-90%) Single example on indole, 61%	25
8		Alkylation			Substrate (1 equiv), 2-vinyl oxirane (1.2 equiv), PivOH (1 equiv), [Cp*Rh(MeCN) ₃]SbF ₆ (3 mol%), Ar, 25 °C, 16 h Single example, 91% (E/Z = 3.1 : 1)	26
9		Alkylation			Substrate (1 equiv), olefine (2 equiv), [RuCl ₂ (p-cymene)] ₂ (1 mol%), O ₂ (1 atm), toluene, 120 °C. The reaction was developed for 2-arylpyridine derivatives (14 examples, 40-94%) Single example on indole, 72%.	27
10		Alkylation	R ¹ -BF ₃ K		Substrate (1 equiv), R ¹ -BF ₃ K (3 equiv), AgF (2.8 - 4 equiv), [Cp*RhCl ₂] ₂ (4 mol%), AgSbF ₆ (16 mol%), DCE, 100 °C, 24 h. R ¹ = Me, <i>n</i> Bu, <i>n</i> Pent, cyclopropyl, cyclopentyl, Bn; R ² = H, OMe; 7 examples, 51-94%.	11

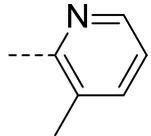
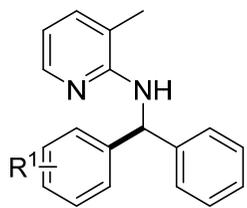
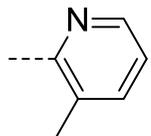
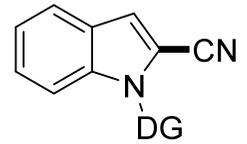
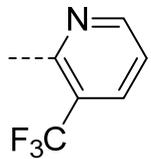
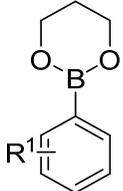
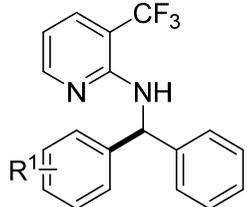
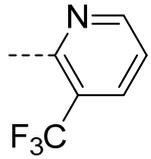
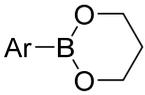
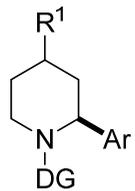
					Many other DGs successfully applied in this contribution	
11		Alkynylation			Substrate (0.2 mmol), R-EBX (0.22 mmol), [RhCp*Cl ₂] ₂ (2 mol%), Zn(OTf) ₂ (0.02 mmol, 10 mol%), DCE (2 mL), 25 or 80 °C, 16 h Single example, 91%.	28
12		Alkynylation			Substrate (1 equiv), alkyne source (1.3 equiv), [Cp*RhCl ₂] ₂ (4 mol%), Cu(OTf) ₂ (20 mol%), DCE, 50 °C, 12 h. R ¹ = TIPS, TES, TBS, TBDPS, tBu, Ph; R ² = H, Me, Ph; R ³ = H, Me, F, Cl, Br; 19 examples, 50-91% DG cleavage: 1) MeOTf, MeCN 2) NaBH ₄ , MeOH	14
13		Amidation			Substrate (1 equiv), phthalimide (1.2 equiv), CuOAc (20 mol%), toluene/o-dichlorobenzene (1:1), 150 °C, O ₂ , 2-3 days. R ¹ = H, Me, MeO, CHO, CN; 5 examples, 31-78%	29
14		Amidation	R-NCO		Substrate (1 equiv), isocyanate (1.1 equiv), [MnBr(CO) ₅] (10 mol%), Et ₂ O, 100 °C, 16 h. R ¹ = H, OMe, F, Br, I, COOMe; R ² = series of aryl and alkyl residues 28 examples, 60-95%	30
15		Amidation			Substrate (1 equiv), dioxazolone (1.2 equiv), Cp*Co(CO)I ₂ (2.5 - 5 mol%), AgSbF ₆ (5 - 10 mol%), NaOAc (5- 10 mol%), DCE, 70-100 °C, 20 h. R ¹ = Ph, 3-MeC ₆ H ₄ , 3-FC ₆ H ₄ , 3-ClC ₆ H ₄ ; R ² = H, MeO, F, Br, I, COOMe; 13 examples, 64-98% 1 example with pyrrole as substrate (55%)	15

16		Arylation			Substrate (1 equiv), boronic acid ester (1.2 equiv), Ru ₃ (CO) ₁₂ (10 mol%), <i>t</i> BuCOMe (5 equiv), 150 °C; 84% Tetrahydroquinoline was also used as substrate and gave 70% yield.	1
17		Arylation	Ph-B(OH) ₂		Substrate (1 equiv), Ph-B(OH) ₂ (2 equiv), Pd(OAc) ₂ (5 mol%), Cu(OTf) ₂ (1 equiv), Ag ₂ O (1 equiv), toluene, 120 °C, 24 h; Single example, 59%	31
18		Arylation			Substrate (1 equiv), boronic acid ester (3-4 equiv), Ru ₃ (CO) ₁₂ (6-8 mol%), 3-ethyl-3-pentanol (1 equiv), reflux, 24 h. 12 examples, Mixtures of mono and bis-arylation products are formed. Cleavage of DG: 1) Pd/C, H ₂ (1 atm), HCl, <i>i</i> PrOH; 2) NH ₂ NH ₂ ·H ₂ O, AcOH, <i>i</i> PrOH.	32
19		Arylation	ArBF ₃ K		Substrate (1 equiv), ArBF ₃ K (4 equiv), Pd(OAc) ₂ (10 mol%), AgOAc (3 equiv), benzoquinone (1 equiv), DMSO (4 equiv), 1,4-dioxane, 130-140 °C, 48 h. R ¹ = H, NO ₂ , MeO; R ² = NO ₂ , CHO, F, Cl, Br, <i>t</i> Bu, Me, COMe; 14 examples, combined yield of both products 45-96% Mixtures of arylation and arylation/cyclization (i.e. carbazoles) products were obtained in ratios between 48:52 – 17:83.	33
20		Arylation			Substrate (1.5 equiv), carbamate (1 equiv), Co(acac) ₂ (10 mol%), IMesHCl (20 mol%), CyMgCl (2 equiv), DMPU, 60 °C, 16 h. R ¹ = F, Me, OMe; R ² = H, Me; 6 examples, 86-94%	10

					Arylation of 2-arylpyridines was the main focus of this paper.	
21		Arylation	ArBF ₃ K		Substrate (1 equiv), ArBF ₃ K (2 equiv), Pd(OAc) ₂ (10 mol%), AgNO ₃ (3 equiv), benzoquinone (1 equiv), tBuOH, 60-70 °C, 24 h. R ¹ = H, NO ₂ , MeO; R ² = H, NO ₂ , Br, MeO, <i>t</i> Bu, COMe; 20 examples, 45-98%. DG cleavage: 1) MeOTf/DCM; 2) 2 M NaOH (aq), MeOH.	34
22		Arylation			Substrate (1 equiv), dienone (1.2 equiv), [Cp*RhCl ₂] ₂ (5 mol%), AgSbF ₆ (30 mol%), Zn(NTf ₂) ₂ (20 mol%), DCE, 100 °C, 20h Single example, 38%	35
23		Benzylation	Ph-CH ₂ -OPO(EtO) ₂		Substrate (1.5 equiv), carbamate (1 equiv), Co(acac) ₂ (10 mol%), IMesHCl (20 mol%), CyMgCl (2 equiv), DMPU, 60 °C, 16 h. Single example, 65% Arylation of 2-arylpyridines was the main focus of this paper.	10
24		Carbonylation	alkene, CO		Indoline (1 mmol), Ru ₃ (CO) ₁₂ (0.05 mmol), CO (initial pressure 10 atm at 25 °C in a 5 ml stainless steel autoclave), alkene (ethylene 5 atm), <i>N,N</i> -dimethylacetamide (3 mL), 160 °C for 20 h; Single example, 41%	36
25		Cyanation	<i>t</i> BuNC		Substrate (1 equiv), <i>t</i> BuNC (3 equiv), Pd(OAc) ₂ (5 mol%), Cu(TFA) ₂ (3 equiv), DMF, O ₂ , 130 °C R ¹ = H, COOMe, OMe, Br, Me; 5 examples, 34-85% In absence of a DG cyanation takes place in position 3 of indole.	12

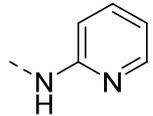
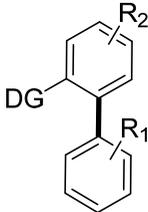
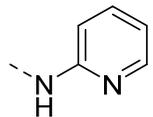
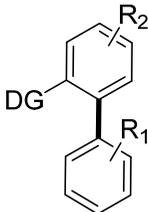
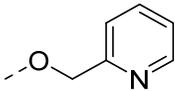
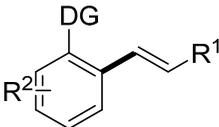
26		Heteroarylation			Indole or pyrrole substrate (1 equiv), N-oxide (4 equiv), Pd(OAc) ₂ (10-20 mol%), DPPB (10-20 mol%), Cu(OAc)H ₂ O (3 equiv), pyridine (2 equiv), 1,4-dioxane, 140 °C, 30 h. Indoles (eventually carrying Cl, Me, MeO) and pyrrole was used as substrate; N-oxides of quinoline, quinoxaline, and pyridine were used; 9 examples, 45-91%	13
27		Imine addition			Substrate (1 equiv), imine (1.08 equiv), [Cp*Rh(CH ₃ CN) ₃]SbF ₆ (5 mol%), <i>t</i> AmylOH, 85 °C, 16 h; 3 examples: R = H (80%), Cl (77%), Br (70%)	37
28		Indole synthesis			Substrate (1.1 equiv), alkyne (1 equiv), Pd/CeO ₂ (5 mol%), CeO 25nm), Cu(TFA) ₂ H ₂ O (20 mol%), DMF, air, 120 °C, 36 h. R ¹ = H, Me, MeO, SMe, COMe, OCF ₃ , COOMe, F, Cl; R ² = aryl; R ³ = aryl or alkyl; 24 examples, 8-99% (typically >90%). Mixed aryl-alkyl alkynes gave predominantly the product with the alkyl in R ³ position.	9
29		Selenylation	PhSeSePh		Substrate (1 equiv), PhSeSePh (1 equiv), Pd(OAc) ₂ (10 mol%), CuBr ₂ (2 equiv), DMF, 80 °C, 48 h. Single example, 53%	38
30		Sulfenylation	PhSSPh		Substrate (1 equiv), PhSSPh (1 equiv), Pd(OAc) ₂ (10 mol%), CuBr ₂ (2 equiv), DMF, 140 °C, 24 h. Single example, 73%	38

31		Trifluoromethylal- ylation			Substrate (1 equiv), alkene (2 equiv), [Cp*RhCl ₂] ₂ (2.5 mol%), AgSbF ₆ (10 mol%), Cu(OAc) ₂ (50 mol%), THF, air, 120 °C, 24 h Single example 66% (16:1 E/Z)	39
32		Alkylation			Substrate (1 equiv), alkene (5 equiv), Ru ₃ (CO) ₁₂ (10 mol%), toluene, 130 °C, 6 h. R ¹ = <i>n</i> Bu, <i>t</i> Bu, cyclohexyl, Ph, Bn C ₈ H ₁₇ ; 8 examples, 60-95% Also cyclopentene and cyclohexene were applied successfully.	18
33		Arylation			Substrate (0.5 mmol), coupling partner (1 mmol), Ru ₃ (CO) ₁₂ (5 mol%), pinacolone (0.5 mL), 140-150 °C, 24 h R ¹ = H, Me, Cl, <i>t</i> Bu, OMe, F, Cl, CF ₃ , COMe; R ² = H, Me, OMe, <i>Oi</i> Pr, F, CF ₃ , COOMe; 15 examples (15-76% yield), NO ₂ , CN were not tolerated DG cleavage: 1) MeMgCl, Boc ₂ O, THF, rt; 2) MeOTf, DCM, 0 °C; 3) NaOH, MeOH, H ₂ O, 50 °C	3,2
34		Arylation	Ar-Br		Substrate (1 equiv), Ar-Br (1.5 equiv), [RuCl ₂ (<i>p</i> -cymene)] ₂ (2.5 mol%), KO ₂ Piv (30 mol%), K ₂ CO ₃ (3 equiv), toluene, 140 °C, 24 h. R ¹ = H, Me, Cl, <i>t</i> Bu, <i>n</i> Bu, NMe ₂ , OMe, F, CF ₃ , COOEt, COMe; R ² = H, Me, OMe, <i>Oi</i> Pr, F, CF ₃ , COOMe 22 examples (28-69% yield), NO ₂ , CN were not tolerated DG cleavage: 1) MeMgCl, Boc ₂ O, THF, rt; 2) MeOTf, DCM, 0 °C; 3) NaOH, MeOH, H ₂ O, 50 °C	6,7

35		Arylation	Ar-Cl		Substrate (1 equiv), Ar-Cl (1.5 equiv), [RuCl ₂ (p-cymene)] ₂ (5 mol%), PPh ₃ (10 mol%), cyclohexanol (1 equiv), K ₂ CO ₃ (3 equiv), toluene, 160 °C, 30 h. R ¹ = H, Me, OMe, COOMe, F, CF ₃ ; 7 examples (30-79% yield); DG cleavage: 1) MeMgCl, Boc ₂ O, THF, rt; 2) MeOTf, DCM, 0 °C; 3) NaOH, MeOH, H ₂ O, 50 °C	6
36		Cyanation	<i>t</i> BuNC		Substrate (1 equiv), <i>t</i> BuNC (3 equiv), Pd(OAc) ₂ (5 mol%), Cu(TFA) ₂ (3 equiv), DMF, O ₂ , 130 °C Single example, 54% In absence of a DG cyanation takes place in position 3 of indole.	12
37		Arylation			Substrate (0.5 mmol), coupling partner (1 mmol), Ru ₃ (CO) ₁₂ (5 mol%), pinacolone (0.5 mL), 140-150 °C, 24 h R ¹ = H, Me, <i>t</i> Bu, OMe, F; 5 examples (51-78% yield) DG cleavage: 1) MeMgCl, Boc ₂ O, THF, rt; 2) MeOTf, DCM, 0 °C; 3) NaOH, MeOH, H ₂ O, 50 °C	3,2
38		Arylation			Substrate (1 equiv), boronic acid ester (4 equiv), Ru ₃ (CO) ₁₂ (7 mol%), CuSO ₄ ·5H ₂ O (2 mol%), 1,3-propanediol (0.5 equiv), <i>o</i> -xylene, 140 °C, 24 h. R ¹ = H, Me, Bn, COOEt; Ar substituents included H, Me, <i>t</i> Bu, F, Cl, MeO, CF ₃ ; 12 examples, 16-60% Cleavage of DG: 1) Pt ₂ O hydrate (5 mol%), H ₂ (1 atm), HCl, <i>i</i> PrOH; 2) silica gel, DCM; 3) NH ₂ NH ₂ ·H ₂ O, AcOH, <i>i</i> PrOH.	5

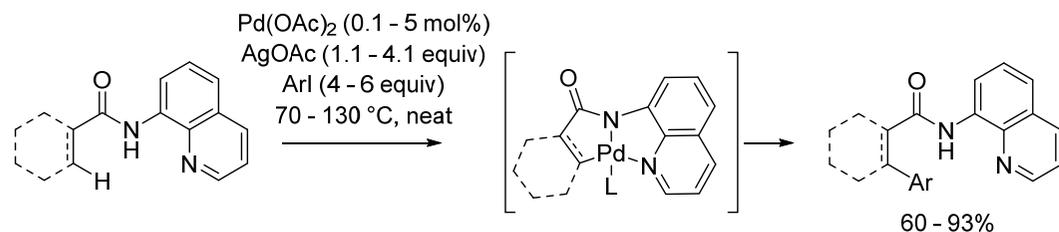
39		Arylation			Substrate (0.5 mmol), coupling partner (1 mmol), Ru ₃ (CO) ₁₂ (5 mol%), pinacolone (0.5 mL), 140-150 °C, 24 h R ¹ = H, Me, Cl, <i>t</i> Bu, F, CF ₃ , COMe; R ² = H, Me, <i>t</i> Bu, F, CF ₃ ; 12 examples (33-96% yield), NO ₂ , CN were not tolerated DG cleavage: 1) MeMgCl, Boc ₂ O, THF, rt; 2) MeOTf, DCM, 0 °C; 3) NaOH, MeOH, H ₂ O, 50 °C	3,2
40		Arylation	Ar-Br		Substrate (1 equiv), Ar-Br (1.5 equiv), [RuCl ₂ (<i>p</i> -cymene)] ₂ (2.5 mol%), KOPiv (30 mol%), K ₂ CO ₃ (3 equiv), toluene, 140 °C, 24 h. R ¹ = H, Me, Cl, <i>t</i> Bu, <i>n</i> Bu, OMe, COOEt, COMe; 9 examples (41-72% yield), NO ₂ , CN were not tolerated DG cleavage: 1) MeMgCl, Boc ₂ O, THF, rt; 2) MeOTf, DCM, 0 °C; 3) NaOH, MeOH, H ₂ O, 50 °C	6,7
41		Arylation	Ar-Cl		Substrate (1 equiv), Ar-Cl (1.5 equiv), [RuCl ₂ (<i>p</i> -cymene)] ₂ (5 mol%), PPh ₃ (10 mol%), cyclohexanol (1 equiv), K ₂ CO ₃ (3 equiv), toluene, 160 °C, 30 h. R ¹ = H, Me, <i>t</i> Bu, <i>n</i> Bu, OMe; 6 examples (39-61% yield); NO ₂ , COMe, COOMe were not tolerated DG cleavage: 1) MeMgCl, Boc ₂ O, THF, rt; 2) MeOTf, DCM, 0 °C; 3) NaOH, MeOH, H ₂ O, 50 °C	6
42		Amidation			Substrate (1 equiv), dioxazolone (1.2 equiv), Cp*Co(CO)I ₂ (2.5 - 5 mol%), AgSbF ₆ (5 - 10 mol%), NaOAc (5- 10 mol%), DCE, 70-100 °C, 20 h. Single example, 92%	15

43		Amidation			Substrate (1 equiv), dioxazolone (1.2 equiv), Cp*Co(CO)I ₂ (2.5 - 5 mol%), AgSbF ₆ (5 - 10 mol%), NaOAc (5- 10 mol%), DCE, 70-100 °C, 20 h. Single example, 97%	15
44		Acylation			Substrate (0.5 mmol), Pd(OAc) ₂ (10 mol%), NHPI (20 mol%), toluene (1 mL) at 80 °C under O ₂ (1 atm) for 24 h. Single example, 43% Much more comprehensive scope on other systems including 2-arylpyridines	40
45		Arylation			Substrate (2-phenoxy pyridine 1 mmol), ArBF ₃ K (2.5 equiv), Pd(OAc) ₂ (10 mmol%), Ag ₂ CO ₃ (2 equiv), <i>p</i> -benzoquinone (1 equiv), DMSO (4 equiv), H ₂ O (8 equiv), DCM, 130 – 40 °C, 48 h; R ¹ = H, NO ₂ , CHO, F, Cl, Br, I, tBu, Me, COMe, COOMe; 12 examples, 7-90%.	41
46		Nitration			Substrate (0.3 mmol), Pd(OAc) ₂ (10 mol%), TBN (2.0 equiv), PhCl (1 mL), at 80 °C under O ₂ (1 atm) for 24 h. R ¹ = H, Me, MeO, I 7 examples, 56-75% yield.	40
47		Nitration			Substrate (0.3 mmol), Pd(OAc) ₂ (10 mol%), TBN (2.0 equiv), PhCl (1 mL), at 80 °C under O ₂ (1 atm) for 24 h. R ¹ = H, Me, MeO, I Single example, 59%	40
48		Nitration			Substrate (0.3 mmol), Pd(OAc) ₂ (10 mol%), TBN (2.0 equiv), PhCl (1 mL), at 80 °C under O ₂ (1 atm) for 24 h. R ¹ = H, Me, MeO, I Single example, 73%	40

49		Arylation	ArB(OH) ₂		<p>Substrate (1 equiv), arylboronic acid (3 equiv), Pd(OAc)₂ (10 mol%), Ag₂O (1 equiv), benzoquinone (0.5 equiv), THF, 80 °C.</p> <p>15 examples, 43-88%; sterically demanding arylboronic acids not well tolerated</p> <p>DG cleavage: 1) Pd/C, H₂ (1 atm), HCl, <i>i</i>PrOH; 2) NH₂NH₂·H₂O, AcOH, EtOH.</p>	8
50		Arylation	ArBF ₃ K		<p>Substrate (1 equiv), ArBF₃K (1.5 equiv), Pd(OAc)₂ (10 mol%), Cu(OAc)₂ (2 equiv), benzoquinone (1 equiv), <i>t</i>BuOH, 80-90 °C, 4 h.</p> <p>R¹ = H, F, Cl, Br, I, NO₂, MeO, CHO, COMe, Me, <i>t</i>Bu; R² = H, F, Cl, Br, NO₂, MeO;</p> <p>20 examples, 45-98%.</p> <p>DG cleavage: 1) MeOTf/DCM; 2) 2 M NaOH (aq), MeOH.</p>	42
51		Alkenylation			<p>Substrate (0.5 mmol), alkene (0.75 mmol), Pd(OAc)₂ (10 mol%), KHCO₃ (2 equiv), Boc-Val-OH (20 mol%), <i>t</i>-AmylOH, 90 °C, 1 atm O₂, 12 h.</p> <p>R¹ = CONMe₂, COOalkyl, aryl; R² = Me, MeO, H, Cl, NO₂;</p> <p>20 examples, 31-95%</p> <p>DG cleavage: Pd/C, H₂ or Mg, MeOH, or BBr₃, DCM, -40 °C - rt</p>	17

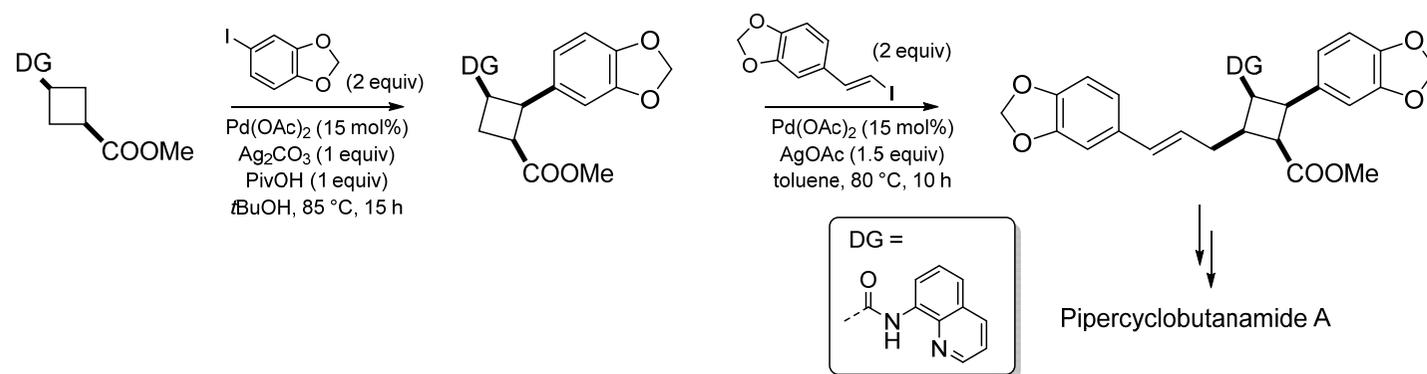
Bidentate heterocyclic directing groups in C-H activation

Due to their versatility and reliability, bidentate directing groups have been heavily used in many types of C-H functionalizations in combination with a broad spectrum of transition-metal based catalysts. Catalytic systems based on *N,N'*- as well as *N,S*-bidentate directing groups have been developed for the functionalization of C(sp³) as well as C(sp²) carbon centers. As shown by van Koten and coworkers in 1993⁴³, bidentate groups promote the activation of C-H bonds *via* the formation of a stable metallacycle.



Scheme 2: Effect of a bidentate directing group.

The most widely used representative is without doubt the aminoquinoline auxiliary. It has been used for the first time in 2005 in a seminal study by Daugulis et al.⁴⁴(Table 2, Entry 62) together with picolinamide and since then was extended to more complex substrates and other coupling partners such as alkyl halides. It was even successfully applied in the total synthesis of celogentin C⁴⁵ or pipericyclobutanamide A⁴⁶ *via* direct C(sp³)-H bond activation.



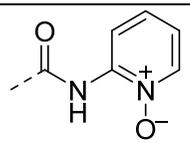
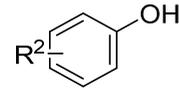
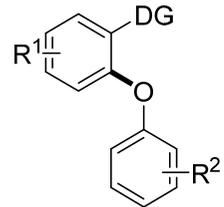
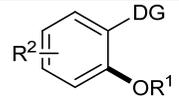
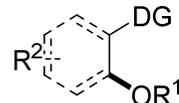
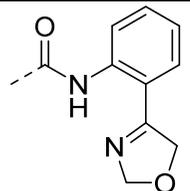
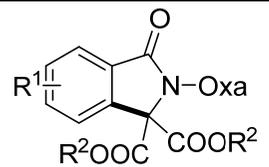
Scheme 3: Application of bidentate directing groups in total synthesis.

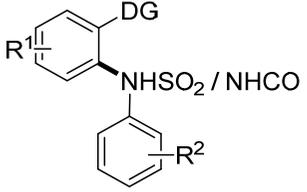
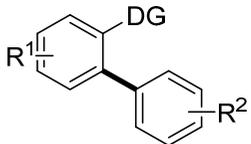
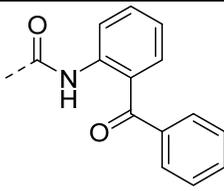
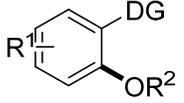
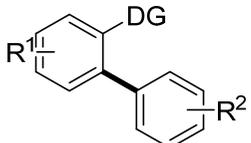
Wang et al.⁴⁷ presented a protocol for the acetoxylation of C(sp³)-carbon centers also at relatively complex starting materials with the potential for late stage functionalization (Table 2, Entry 27).

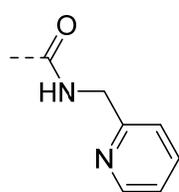
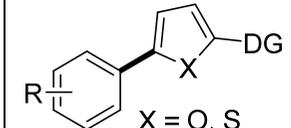
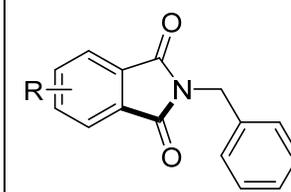
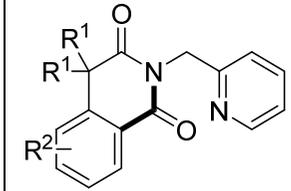
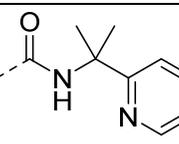
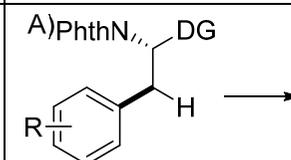
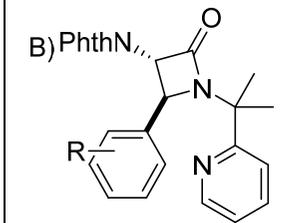
Significant progress has been made in the replacement of precious metals by less expensive ruthenium- nickel- or iron- based systems. In 2012, the Ru(II)-catalyzed arylation of *ortho* C(sp²)-H bonds in aromatic amides was presented (Table 2, Entry 64).⁴⁸ The presence of the bidentate aminoquinolineamide directing group was reported as crucial for the reaction to proceed also in the Ru-catalyzed alkylation of α,β -unsaturated ketones (Table 2, Entry 46).⁴⁹ The first Ni(II)-catalyzed *ortho*-alkylation of benzamides was published shortly after by the same authors (Table 2, Entry 38).⁵⁰ The double chelating aminoquinolineamide and picolinamide have been utilized by Nakamura and coworkers⁵¹ for the C(sp²) and C(sp³) alkylation (Table 2, Entry 34). A remarkable robust setup has been presented by the Cook group (Table 2, Entry 35).⁵² The *ortho*-benzylation of various aromatic or olefinic substrates was achieved on gram- scale in air.

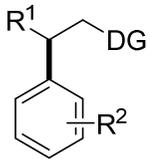
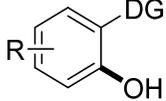
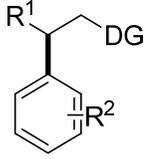
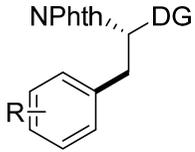
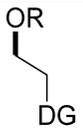
The effects of bidentate directing groups have recently been reviewed in more detail elsewhere.⁵³⁻⁵⁵

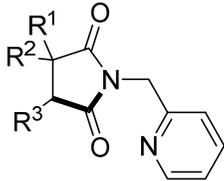
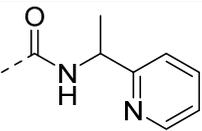
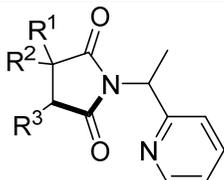
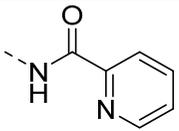
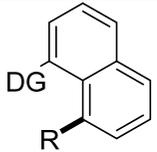
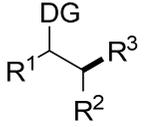
Table 2: Bidentate heterocyclic directing groups

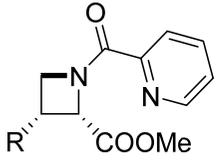
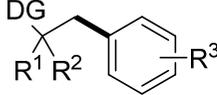
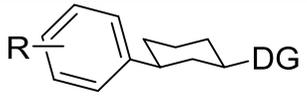
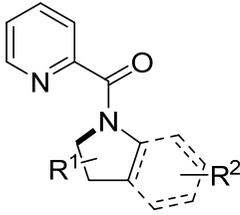
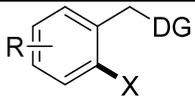
Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
1		Aryloxylation			Substrate (0.2 mmol), phenol (0.6 mmol), Cu(OAc) ₂ (1 equiv), Cs ₂ CO ₃ (1 equiv), <i>o</i> -xylene (1 mL), 130 °C, 8 h, air 24 examples, selective mono- or diaryloxylation possible, yields between 55 and 75% R ¹ = Me, halogen, OMe, CF ₃	⁵⁶
2		Alkoxylation	R ¹ OH		Substrate (0.2 mmol), R ¹ OH (0.75 mL), CuCl (0.2 mmol), K ₂ CO ₃ (0.1 mmol), pyridine (0.75 mmol), 130 °C, air, 12 h 40 examples, 38-94% yield R ¹ = Alkyl R ² = OMe, Me, CF ₃ , COOMe, SO ₂ Me, NO ₂ , halogen	⁵⁷
3		Alkoxylation	R ¹ OH		Substrate (0.2 mmol), R ¹ OH (1.5 mL), Co(OAc) ₂ ·H ₂ O (20 mol%), Ag ₂ O (0.2 mmol), NaOPiv·H ₂ O (2 equiv), argon, 40 °C, 12 h 33 Examples, 34-83% yield R ¹ = Alkyl, Bn R ² = OMe, Me, CF ₃ , NMe ₂ , halogen	⁵⁸
4		Alkylation / Cyclization	Malonate		Substrate (0.1 mmol), malonate (0.2 mmol), Cu(OAc) ₂ (20 mol%), Li ₂ CO ₃ (0.1 mmol), Ag ₂ CO ₃ (0.15 mmol), DMSO (4 mL), air, 80 °C, 12 h 20 examples, 40-72% yield R ¹ = Halogen, Me, OMe, ^t Bu, Ac, CF ₃ R ² = Me, Et	⁵⁹

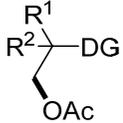
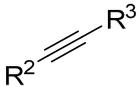
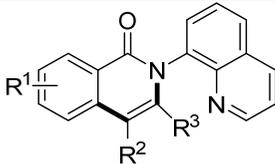
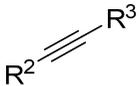
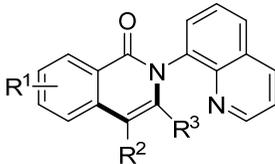
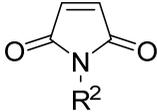
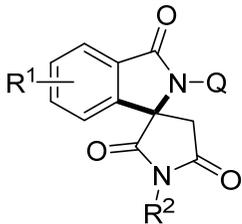
5		Amidation	$R^2SO_2NH_2 / R^2CONH_2$		<p>Substrate (0.1 mmol), sulfonamide / amide (0.2 mmol), $Cu(OAc)_2$ (0.1 mmol), Na_2CO_3 (0.2 mmol), DMSO (1 mL), 80 °C, air, 6 h</p> <p>38 Examples, 9-85% yield</p> <p>R^1 = Aryl, vinyl, halogen, Me, OMe</p> <p>R^2 = Me, OMe, halogen, NO_2, COOMe</p>	⁶⁰
6		Arylation	ArBPIn		<p>Substrate (1 mmol), arylboronate (0.25 mmol), $Cu(OAc)_2$ (0.03 mmol), Ag_2O (0.15 mmol), Na_2CO_3 (0.2 mmol), KOAc (0.2 mmol), DMSO (1 mL), 70 °C, 4 h</p> <p>28 Examples, 26-70% yield</p> <p>R^1 = Aryl, vinyl, halogen, Me, OMe</p> <p>R^2 = Me, OMe, halogen, NO_2, COOMe</p>	⁶¹
7		Acetoxylation/ Methoxylation	$Ac_2O / MeOH$		<p>Acetoxylation: Substrate (1 mmol), $PhI(OAc)_2$ (1 mmol), $Pd(OAc)_2$ (0.1 mmol), AcOH (0.5 mL), Ac_2O (0.5 mL), 110 °C, N_2</p> <p>Methoxylation: Substrate (1 mmol), $PhI(OAc)_2$ (1 mmol), $Pd(OAc)_2$ (0.1 mmol), MeOH (0.5 mL), 110 °C, N_2</p> <p>14 examples, 30-85% yield</p> <p>R^1 = Me, OMe, OPh, NO_2, halogen</p> <p>R^2 = Ac, Me</p> <p>- <i>o</i>-NO_2 is not tolerated</p>	⁶²
8		Arylation	ArI		<p>Substrate (1 mmol), iodoarene (3 mmol), $AgOAc$ (1 mmol), $Pd(OAc)_2$ (0.1 mmol), 110 °C</p> <p>14 Examples, 65-90% yield</p> <p>R^1 = Me, OMe, NO_2, F</p> <p>R^2 = Me, OMe, C(O)Me,</p>	⁶³

9		Arylation	ArBr	 X = O, S	<p>Substrate (1.5 equiv), aryl bromide (1 equiv), PdCl(C₃H₅)(dppb) (0.5 mol%), KOAc (2 equiv), DMAc, 150 °C, 16 h</p> <p>16 examples, also <i>N-n</i>-propylamide possible, no electron rich coupling partners investigated</p> <p>R = C(O)Me, CHO, CN, CF₃, F; pyridine tolerated</p> <p>- Authors state under these reaction conditions, amide does not function as directing group</p>	64
10		Carbonylation	CO, ethylene		<p>Substrate (1 equiv), Ru₃(CO)₁₂ (5 mol%), CO (10 atm), ethylene (7 atm), H₂O (2 equiv), toluene, 160 °C, 24 h</p> <p>16 Examples, 60-89% yield</p> <p>R = Me, OMe, NMe₂, COOMe, C(O)Me, CN, Cl, Br</p> <p>open chain product not observed</p>	65
11		Carbonylation	CO		<p>Substrate (1 mmol), CO (10 atm), ethylene (7 atm), H₂O (2 mmol), Ru(CO)₁₂ (0.05 mmol), toluene (3 mL), 160 °C, 24 h</p> <p>9 examples, 41-93% yield</p>	66
12		Arylation	ArI	<p>A) </p> <p>B) </p>	<p>A)</p> <p>Substrate (0.2 mmol), iodoarene ((0.3 mmol), Pd(OAc)₂ (10 mol%), CuF₂ (0.3 mmol), DMPU (1 mmol), acetone (2 mL), N₂, 100 °C, 24 h</p> <p>17 Examples, 35-89% yield</p> <p>R = Me, OR, Halogen, NHAc, NO₂</p> <p>B) -</p> <p>A (0.15 mmol), Pd(OAc)₂ (10 mol%), NaIO₃ (0.3 mmol), Ac₂O (1.5 mmol), CH₃CN (3 mL), N₂, 70 °C, 48 h</p> <p>17 Examples, 46-85% yield</p>	67

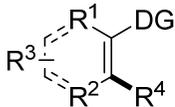
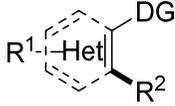
					- diastereoselective	
13		Arylation	ArBr		<p>Substrate (0.15 mmol), bromoarene (0.15 mmol), Pd(OAc)₂ (10 mol%), K₂CO₃ (2.5 equiv), PivOH (0.2 equiv), <i>t</i>-BuOH (1.5 mL), 120 °C, 24 h</p> <p>40 Examples, 23-89% yield</p> <p>R¹ = Alkyl, Aryl</p> <p>R² = Me, Halogen, CF₃, CN, COOR, NO₂, NHAc, OR</p>	⁶⁸
14		Hydroxylation	Cu(OAc) ₂		<p>Substrate (0.2 mmol), Cu(OAc)₂ (0.2 mmol), Ag₂CO₃ (0.4 mmol), tetrabutylammonium iodide (0.4 mmol), DMF (2 mL), 100 °C, 1 h</p> <p>15 Examples, 31-93% yield</p> <p>R = OMe, Me, CF₃, halogen, NO₂, NHAc</p>	⁶⁹
15		Arylation	ArBr		<p>Amide (0.15 mmol), Pd(OAc)₂ (0.1 mol%), K₂CO₃ (2.5 equiv), PivOH (0.2 equiv), <i>t</i>-BuOH (1.5 mL), 120 °C, 24 h</p> <p>40 Examples, 27-89% yield</p> <p>R¹ = Aryl, heteroaryl, alkyl</p> <p>R² = Me, F, OMe, CN, CF₃, COOR, NO₂, NHAc</p>	⁶⁸
16		Arylation/Amidation	ArI		<p>Amide (0.2 mmol), aryl iodide (1.5 equiv), Pd(OAc)₂ (10 mol%), CuF₂ (0.3 mmol), DMPU (1 mmol), acetone (2 mL), N₂, 100 °C, 24 h</p> <p>21 Examples, 35-82% yield</p> <p>R = Me, ^tBu, halogen, OMe, NHAc</p>	⁶⁷
17		Alkoxylation	ROH		<p>Amide (0.2 mmol), Pd(OAc)₂ (10 mol%), PhI(OAc)₂ (1.5 equiv), alcohol/<i>m</i>-xylene (1/1, 2 mL), 90 °C, 24 h; 14 – 90% yield</p>	⁷⁰

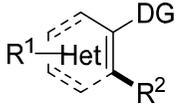
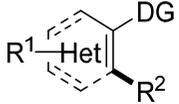
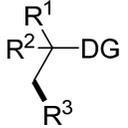
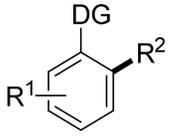
18		Carbonylation	CO		<p>Substrate (1 mmol), CO (10 atm), ethylene (7 atm), H₂O (2 mmol), Ru₃(CO)₁₂ (0.05 mmol), toluene (3 mL), 160 °C, 5 days</p> <p>15 Examples; Yield: 52-83%</p> <p>R¹ = Alkyl, Bn R² = Alkyl R¹-R³ = -(CH₂)- R¹-R² = -(CH₂)₅-</p>	71
19		Carbonylation	CO		<p>Substrate (1 mmol), CO (10 atm), ethylene (7 atm), H₂O (2 mmol), Ru₃(CO)₁₂ (0.05 mmol), toluene (3 mL), 160 °C, 5 days</p> <p>6 Examples; Yield: 14-81%</p> <p>R¹ = Alkyl, Bn R² = Alkyl R¹-R³ = -(CH₂)₁₋₂-</p>	71
20		Alkylation	RI		<p>Substrate (0.25 mmol), Pd(OAc)₂ (15 mol%), KOAc (2 equiv), 1,4-dioxane or xylene (5 mL), 130 °C</p> <p>11 examples, 15-82% yield</p> <p>R = Alkyl, Bn</p>	72
21		Alkylation, Arylation	R ³ X (X=Br, I)		<p>Substrate (0.74 mmol), Pd(OAc)₂ (5 mol%), K₂CO₃ (2.5 equiv), pivalic acid (2 equiv), alkyl bromide or iodide (4 equiv), 'Amyl-OH solvent, 24 h, 110 °C.</p> <p>15 Examples; Yield: 29-91%</p> <p>R¹- R² = Alkyl R² = Aryl R³ = Aryl, Alkyl</p>	73

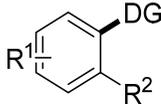
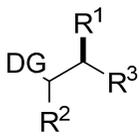
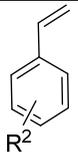
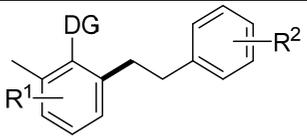
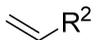
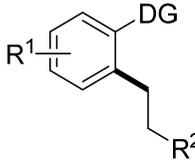
22		Intramolecular Amination			Substrate (1 equiv), Pd(OAc) ₂ (5 mol%), PhI(OAc) ₂ (2.5 equiv), AcOH (2 equiv), toluene, Ar, 110 °C, 24 h 6 Examples, 25-91%, R = Alkyl, O ^t Bu	⁷⁴
23		Arylation	ArI		Substrate (0.1 mmol), iodoarene (0.2 mmol), Pd(OTFA) ₂ (10 mol%), Ag ₃ PO ₄ (0.09 mmol), TBB (1 mL), 100 °C, 3 h 14 examples, 40-84% yield R ¹ = Alkyl R ² = Alkyl R ³ = Alkyl, OR, Halogen, OAc - ortho-substitution not tolerated	⁷⁵
24		Arylation	ArI		Substrate (1 equiv), aryl iodide (1.5 equiv), Pd(OAc) ₂ (0.1 equiv), Ag ₂ CO ₃ (1 equiv), <i>t</i> BuOH, 80 °C, 24 h 6 Examples, 31-81% yield R = OMe, COOMe, NO ₂ , OTIPS also alkene iodides possible (110 °C required) - Stereoselective formation of arylated cyclohexane derivatives	⁷⁶
25		Intramolecular Cyclization			Substrate (1 equiv), Pd(OAc) ₂ (5 mol%), PhI(OAc) ₂ (2 equiv), 80-120 °C, toluene, 24 h 14 Examples, 16-86% yield R ¹ = Alkyl R ² = Cl, OMe Formation of pyrrolidine, indoline and isoindoline possible,	⁷⁷
26		Halogenation	NaXO ₃		Iodination: Substrate (1 equiv), KIO ₃ (2 equiv), K ₂ S ₂ O ₈ (2 equiv), Pd(OAc) ₂ (10 mol%), <i>n</i> -BuOH, 120 °C, 24 h 6 Examples, 43-73% yield	⁷⁸

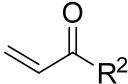
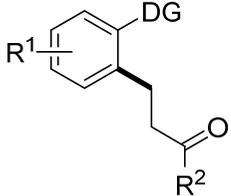
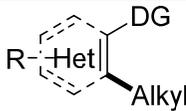
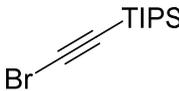
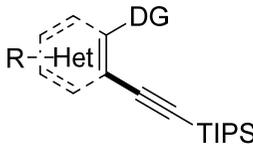
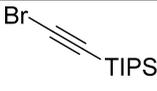
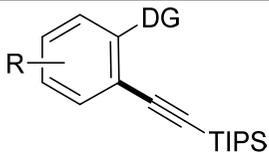
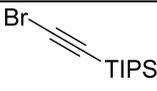
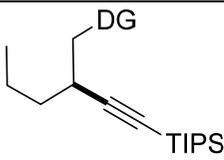
					Bromination/Chlorination: Substrate(1 equiv), NaX (1.5 equiv), NaXO ₃ (1.5 equiv), K ₂ S ₂ O ₈ (2 equiv), Pd(OAc) ₂ (10 mol%), n-BuOH, 100-110 °C, 24 h 12 Examples, 20-65% yield	
27		Acetoxylation	AgOAc		Substrate (1 equiv), Cu(OAc) ₂ (1 equiv), AgOAc (5 equiv), NaOAc (1 equiv), NMP, 145 °C, 24h. 19 Examples, Yield 39-87%; up to 38% bis-acetoxylation R ¹ = Alkyl, CF ₃ , aryl R ² = Alkyl	47
28		Alkenylation / Cyclization			Substrate (0.4 mmol), alkyne (0.8 mmol), [RuCl ₂ (<i>p</i> -cymene) ₂] (5 mol%), Cu(OAc) ₂ ·H ₂ O, <i>t</i> AmOH, 110 °C, 24h. R ¹ = OMe, Halogen, NO ₂ , CN, Me, CF ₃ , <i>t</i> Bu R ² = Aryl, Alkyl R ³ = Aryl, Alkyl	79
29		Alkenylation / Cyclization			Substrate (0.5 mmol), alkyne (1.2 equiv), Co(OAc) ₂ ·4H ₂ O (10 mol%), NaOPiv (2 equiv), Mn(OAc) ₂ (1 equiv), CF ₃ CH ₂ OH (5 mL), 80 °C, 16 h 18 Examples; Yield: 64-96% R ¹ = CF ₃ , I, Br, NO ₂ , Me, OMe; thiophene and furan tolerated R ² = Ph, CH ₂ OH, Me, H R ³ = CH ₂ OH, alkyl, Ph, COOEt, TIPS, CH ₂ NPhth	80
30		Alkenylation / Intramolecular Cyclization			Substrate (0.25 mmol), maleimide (1.0 mmol), Cu(OAc) ₂ (1 mmol), PivOH (0.25 mmol), Cy ₂ NMe (1 mmol), DMF (1.5 mL), 80 °C, 24 h, N ₂ . 16 examples, 19-99 % yield R ¹ = Me, OMe, Cl, CF ₃	81

					$R^2 = \text{Me, Bn, Ph}$	
31		Alkenylation			Substrate (0.4 mmol), borate (4 equiv), Fe(acac) ₃ (10 mol%), dppen (10 mol%), ZnBr ₂ ·TMEDA (20 mol%), DCIB (200 mol%), THF, 70 °C, 24 h 41 Examples; Yield: 51-96% $R^1 = \text{Alkyl, aryl,}$ $R^2 = \text{Alkene, aryl, heteroaryl}$	82
32		Alkenylation			Substrate (0.6 mmol), alkyne (0.2 mmol), Ni(OAc) ₂ (30 mol%), PPh ₃ (60 mol%), <i>i</i> PrOH (0.1 mL), toluene (0.5 mL), 170 °C, 24 h 18 Examples; Yield: 64-84% $R^1 = \text{Me, -(CH2)4-5-}$ $R^2 = \text{Aryl, heteroaryl, alkyl}$ $R^3 = \text{Aryl, heteroaryl}$	83
33		Alkenylation, Alkynylation, Arylation	RI		Substrate (1 equiv), RI (3 equiv), AgOAc (3 equiv), Pd(OAc) ₂ (5-40 mol%), toluene, 80-100 °C 6 Examples; Yield: 77-98% $R = \text{Aryl, alkene, alkyne}$ applicable to synthesis of piperarborenines	84
34		Alkylation	AlR^2_3		Substrate (0.5 mmol), AlR^2_3 (2 equiv, 2M sol. in hexane), Fe(acac) ₃ (10 mol-%), Ph-dppen (11 mol-%), 2,3-DCB (4 equiv), THF, 70 °C, 24h. $R1 - R2 = \text{Alkyl}$	51
35		Alkylation	R^2X		Benzylation: Substrate (1 equiv), benzylchloride (3-3.5 equiv), (Fe(acac) ₃ (10-15 mol%), dppe (15-20 mol%), PhMgBr (3.25-4.1 equiv), THF, 65 °C, 8-10 min, under air or N ₂ .	52

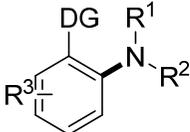
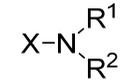
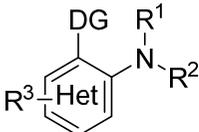
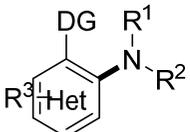
					<p>16 Examples; Yield: 41-91%</p> <p>R¹ = Alkyl, halogen, CF₃, SMe, NMe₂, OMe; thiophene and pyrrole tolerated</p> <p>Alkylation: Fe(acac)₃ (10 mol%), dppe (11 mol%), R²X (secondary) (2.0 equiv), PhMgBr (4.1 equiv), BHT in THF, 65 °C, 5 min, under air or N₂.</p> <p>10 Examples; 26-73%</p> <p>R² = Secondary alkyl</p>	
36		Alkylation	R ⁴ X (X= Br, I, OTs)		<p>Substrate (0.4 mmol), <i>p</i>-AnisMgBr (3 equiv), ZnBr₂·TMEDA (2 equiv), alkyl bromide or iodide (1.2–1.5 equiv), Fe(acac)₃ (10 mol%), dppen (10 mol%), NaI (1.5 equiv), THF, 50–70 °C, 9–12 h</p> <p>33 Examples; Yield: 12-93%</p> <p>R¹–R²= Aryl</p> <p>R¹–R² = Alkyl</p> <p>R³ = Me, OMe, NMe₂, halogen; thiophene and indole tolerated</p> <p>R⁴ = Alkyl</p>	85
37		Alkylation	R ² MgCl		<p>Substrate (1 equiv), RMgCl (4 equiv), ZnCl₂·TMEDA (3 equiv), Fe(acac)₃/dppen (10 mol%), DCIB (2 equiv), THF, 70 °C, 15 h.</p> <p>27 Examples; Yield. 51-99%</p> <p>R¹ = Me, OMe, halogen, NMe₂; furan, thiophene, indole tolerated</p> <p>R² = Alkyl</p>	86

38		Alkylation	R ² Br		<p>Substrate (0.3 mmol), RBr (0.6 mmol), Ni(OTf)₂ (10 mol%), PPh₃ (20 mol%), and Na₂CO₃ (2 equiv), toluene (1 mL), 140 °C, 24 h</p> <p>33 Examples; Yield: 50-95%</p> <p>R¹ = OR, Me, Ph, C(O)Me, CF₃, halogen; heterocyclic and olefinic substrates tolerated</p> <p>R² = Alkyl</p>	50
39		Alkylation	ArI		<p>Substrate (0.3 mmol), ArI (0.6 mmol), Ni(OTf)₂ (5-10 mol%), NaHCO₃ (0.6 mmol) in toluene (1 mL) at 160 °C for 20 h</p> <p>R¹ = F, Ph, CF₃, NMe₂, OMe, Me, halogen, C(O)Me; thiophene tolerated</p>	87
40		Alkylation	R ³ X X = I or Br		<p>Substrate (0.3 mmol), RX (5.0 equiv), Ni(acac)₂ (10 mol%), dppbz (10 mol%), Cs₂CO₃ (5.0 equiv), N₂ (1 atm), 1.2 mL toluene, 150 °C, 12–24 h.</p> <p>26 Examples; Yield: 61-91%</p> <p>R¹ = Alkyl, benzyl, Ph</p> <p>R² = Alkyl</p> <p>R³ = Alkyl</p>	42
41		Alkylation	R ² X (X=Br, I)		<p>Substrate (0.74 mmol), Pd(OAc)₂ (5 mol%), K₂CO₃ (2.5 equiv), pivalic acid (20 mol%), alkyl bromide or iodide (3–4 equiv), 'Amyl-OH, 12–96 h, 100–110 °C.</p> <p>16 Examples; Yield: 22-94%</p> <p>R¹ = Br, <i>t</i>Bu, CF₃, OMe</p> <p>R² = Aryl, alkyl</p> <p>mostly bisarylation</p>	73

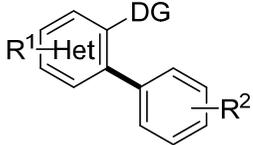
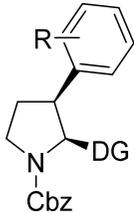
42		Alkylation	Alkyl iodide		<p>Monoarylation: Substrate (0.2 mmol), alkyl iodide (3 equiv), NaHCO₃ (2 equiv), BP (0.3 equiv), Pd(OAc)₂ (5 mol%), 110 °C, 20 h, Ar</p> <p>8 Examples; Yield: 75-87%</p> <p>R¹ = OMe, Me, CF₃</p> <p>R² = Alkyl, benzyl</p> <p>Diarylation: Substrate (0.2 mmol), alkyl iodide (4 equiv), NaHCO₃ (3.5 equiv), BP (0.3 equiv), Pd(OAc)₂ (5 mol%), O₂, 110 °C, 20 h</p> <p>4 Examples; Yield: 82%</p> <p>Also bromides and chlorides applicable</p>	88
43		Alkylation, Arylation	R ¹ I		<p>Substrate (1 equiv), Ri (3-4 equiv), Pd(OAc)₂ (0.05 equiv), base (2.5-3.5 equiv), <i>t</i>-AmOH</p> <p>13 Examples; Yield: 45-81%</p> <p>R¹ = Alkyl, aryl</p> <p>R² – R³ = Alkyl, aryl</p> <p>bisarylation was observed</p>	89
44		Alkylation			<p>Substrate (0.3 mmol), styrene (2 equiv), [Rh(OAc)(cod)]₂ (2.5 mol%), PivOH (1 equiv), toluene (1 mL), 160 °C, 12 h</p> <p>19 Examples; Yield: 39-90%</p> <p>R¹ = OMe, Me, F, OAc, CF₃; thiophene tolerated</p> <p>R² = OMe, alkyl, Ph</p> <p>Heck type reaction is suppressed by addition of PivOH.</p>	90
45		Alkylation			<p>Substrate (0.3 mmol), alkene (0.6 mmol), [RhCl(cod)]₂ (2.5 mol%), KOAc (25 mol%), toluene (1 mL), 160 °C, 12 h</p> <p>24 Examples; Yield: 48-91%</p> <p>R¹ = Me, OMe, Ph, CF₃, F, Ac, Br; heterocycles tolerated</p>	91

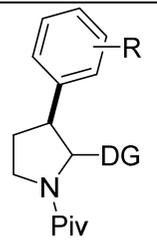
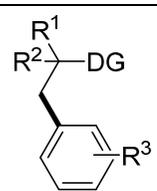
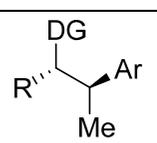
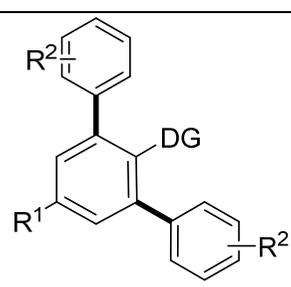
					$R^2 = \text{COOR}, \text{SO}_2\text{Ph}$	
46		Alkylation			<p>Substrate (0.5 mmol), vinyl ketone (2 equiv), $[\text{RuCl}_2(\text{p-cymene})]_2$ (10 mol%), NaOAc (25 mol%), toluene (1 mL), 100 °C, 4-6 h.</p> <p>43 Examples; Yield: 16-96%</p> <p>$R^1 = \text{Me}, \text{Ph}, \text{CF}_3, \text{OMe}, \text{F}, \text{COOMe}, \text{halogen}, \text{NMe}_2, \text{OCF}_3, \text{OAc}$; heterocycles tolerated</p> <p>$R^2 = \text{Alkyl}, \text{aryl}$</p> <p>Bisarylation up to 70%</p>	49
47		Alkylation	alkyl halide		<p>Substrate (1 equiv), alkyl halide (3 equiv), PhMgBr (3.45 equiv), $[\text{Fe}(\text{acac})_3]$ (10 mol%), dppe (15 mol%), 2-Me-THF (1 M), 65 °C, 9 min</p> <p>33 Examples; Yield: 31-90%</p> <p>$R = \text{Alkyl}, \text{halogen}, \text{CF}_3, \text{OMe}, \text{NMe}_2$; pyrrole tolerated</p>	92
48		Alkynylation			<p>Substrate (0.2 mmol), alkyne (1.2 equiv), NiCl_2 (10 mol%), BDMAE (40 mol%), Na_2CO_3 (5 equiv), toluene (2 mL), 100 °C, 24 h</p> <p>25 Examples, 33-95% yield</p> <p>$R = \text{Halogen}, \text{NO}_2, \text{OMe}, \text{CF}_3, \text{Me}, \text{Ac}$</p>	93
49		Alkynylation			<p>Substrate (0.3 mmol), alkyne (1.2 equiv), $\text{Pd}(\text{OAc})_2$ (5 mol%), CsOAc (1 equiv), toluene (0.6 mL), 110 °C, 15 h</p> <p>14 Examples; Yield: 66-92%</p> <p>$R = \text{Me}, \text{OR}, \text{NMe}_2, \text{Br}, \text{CF}_3, \text{COOMe}$; thiophene tolerated</p>	94
50		Alkynylation			<p>Substrate (0.21 mmol), alkyne (1.5 equiv), SAuPd, AgOAc (1.2 equiv), LiCl (2 equiv), 135 °C</p> <p>Yields: 80%</p> <p>Pd immobilized on SAuPd, recyclable for up to 10 times</p>	95

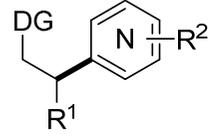
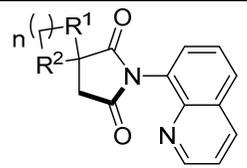
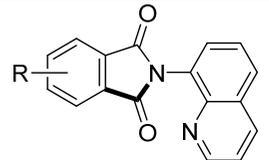
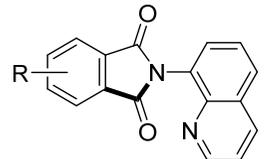
51		Allylation			Substrate (0.4 mmol), allyl phenyl ether (1.2 equiv), Fe(acac) ₃ (5 mol%), dppen (5 mol%), ZnCl ₂ ·TMEDA (1.2 equiv), ^t BuCH ₂ MgBr (3.4 equiv), 4 h, 70 °C 15 Examples; Yield: 61-97% R = Me, OMe, halogen, CF ₃ , COOMe; heterocycles and polyaromatic compounds tolerated	⁹⁶
52		Amidation / Intramolecular Cyclization	-		Substrate (0.3 mmol), [Ni(dme) ₂ I ₂] (10 mol%), TEMPO (3 equiv), K ₂ HPO ₄ (2 equiv), TBAI (0.1 equiv), <i>n</i> PrCN/PhCN (1.5 mL, 3:2, v/v), 150 °C, 24 h. 25 examples, 11-93% yield R ¹ = Alkyl, Ph, Bn, CH ₂ OAc R ² = Alkyl n = 2-4	⁹⁷
53		Amidation (Intramolecular)			Substrate (0.2 mmol), Pd(OAc) ₂ (5 mol%), PhI(OAc) ₂ (2.5 equiv), toluene, 70-110 °C, Ar, 24 h. 7 Examples, Yield: 65-94% R ¹ = Me, ^t BuO R ² = NHPht, H	⁹⁸
54		Amidation (Intramolecular Cyclization)	-		Substrate (1 equiv), Cu(OAc) ₂ (20 mol%), Ag ₂ CO ₃ (3.0 equiv), DCE, 140 °C, 24h. 18 examples, 51-93% yield R ¹ = Alkyl, Ph, Bn, CF ₃ R ² = Me, Et R ³ = Aryl	⁹⁹
55		Amination			Substrate (0.2 mmol), amine (0.4 mmol), Ni(OAc) ₂ (10 mol%), Ag ₂ CO ₃ (0.4 mmol), Na ₂ CO ₃ (0.4 mmol), toluene (2.0 mL), 140 °C, air, 10 h.	¹⁰⁰

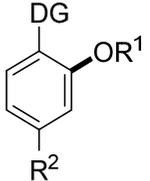
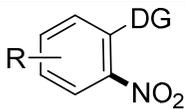
					<p>31 Examples; Yield: 44-80%</p> <p>$R^1 - R^2 =$ Morpholine, Alkyl</p> <p>$R^3 =$ Alkyl, OMe, Ph, NMe₂, F, Cl, Br, CF₃</p> <p>thiophene tolerated</p>	
56		Amination			<p>Substrate (0.5 mmol), amine (2 equiv), Cu(BTC) (25 mol%), NMO (2 equiv), NMP, 90 °C, 6h.</p> <p>12 Examples; Yield: 40-85%</p> <p>$R^1 - R^2 =$ Morpholine, piperidine, pyrrolidine</p> <p>$R^1 =$ "Hex, Ph, Bn</p> <p>$R^2 =$ Me, H</p> <p>$R^3 =$ OMe, Me, CF₃</p>	101
57		Amination	 <p>X = Cl or OBz</p>		<p>Substrate (1 equiv), PhMgBr/ THF (3.2–3.4 equiv), Fe(acac)₃ (10 mol%), and F-dppbz (15 mol%), amine (2.7 equiv), 65 °C.</p> <p>22 Examples; Yield: 54-99%</p> <p>$R^1 - R^2 =$ Morpholine</p> <p>$R^1 =$ Alkyl</p> <p>$R^2 =$ Alkyl, benzyl</p> <p>$R^3 =$ Me, OMe, CF₃, halogen, NMe₂</p> <p>thiophene and indole tolerated</p>	102
58		Amination			<p>Substrate (0.5 mmol), Cu(OAc)₂ (10-25 mol%), Ag₂CO₃ (12-25 mol%), NMP (2 mL), 110 °C, 11-25h</p> <p>20 examples; Yield: 20-87%</p> <p>$R^1 =$ H, Me</p> <p>$R^2 =$ Bn, alkyl</p> <p>$R^3 =$ OMe, F, CF₃, alkyl, COOMe</p> <p>heterocycles tolerated</p>	103

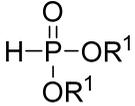
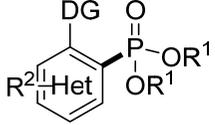
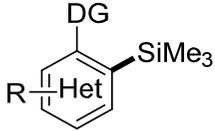
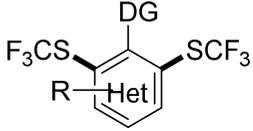
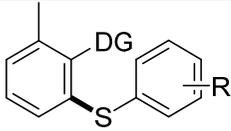
59		Amino-Alkenylation			Substrate (0.4 mmol), ethyl cyanate (1.2 mmol), Cu(OAc) ₂ (1.2 mmol), Na ₂ CO ₃ , DMSO, 90 °C, 4–6 h, Ar. 24 examples, 49-95% yield R ¹ = COOR, CON(Me) ₂ , SO ₂ CH ₃ , PO(OEt) ₂	104
60		Arylation	ArBr		Substrate (0.3 mmol), ArBr (1.2 mmol), Pd(TFA) ₂ (0.015mmol), K ₂ CO ₃ (1.05 mmol), PivOH (0.15 mmol), tAmyl-OH (0.5mL), 120 - 140 °C, 36 h 24 Examples; Yield: 9-94% R ¹ = H, alkyl R ² = Alkyl, Ph R ³ = OMe, Me, halogen, Ph, CN, NO ₂ , CHO, CF ₃ , OCF ₃ , OH, NHCOMe; heterocycles tolerated	105
61		Arylation			Substrate (0.3 mmol), diaryliodonium salt (0.36 mmol), Ni(OTf) ₂ (0.03 mmol), Na ₂ CO ₃ (0.6 mmol), MTHP (1 mL), 140 °C, 24 h 20 Examples; Yield: 11-93% (NMR yields) R ¹ = Ph, Bn, alkyl R ² = Ph, alkyl R ³ = CF ₃ , COOMe, Ac, NO ₂ , Cl, OMe, Me	106
62		Arylation	ArI		Substrate (1 equiv), ArI (4-6 equiv), Pd(OAc) ₂ (0.1-5 mol%), AgOAc (1.1-4.1 equiv), 70-130 °C, 5 min-16 h 5 Examples; Yield: 60-93% R ¹ = Alkyl R ² = Ph, alkyl	44
63		Arylation	ArI		<i>cis</i> -Substrate: Substrate (0.05 mmol), ArI (3 equiv), Pd(OAc) ₂ (10 mol%), AgOAc (1.5 equiv), toluene (0.2 M), 80 °C, 6 h.	107

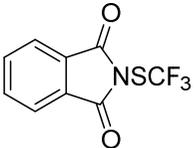
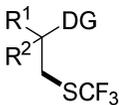
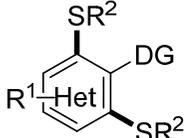
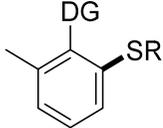
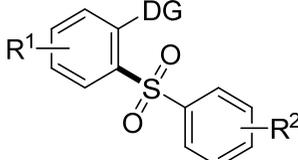
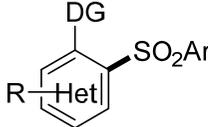
					<p>14 Examples; Yield: 39-95%</p> <p>R = C(O)Me, COOMe, OMe, halogen, CHO, CH₂OH; heterocycles tolerated</p> <p><i>trans</i>-Substrate: Substrate (0.05 mmol), ArI (3 equiv), Pd(OAc)₂ (10 mol%), AgOAc (1.5 equiv), K₃PO₄ (1 equiv), toluene (0.2 M), 80 °C, 6 h.</p> <p>10 Examples; Yield: 31-71%</p> <p>R = C(O)Me, COOMe, OMe, halogen, CHO, CH₂OH, CN, halogen; heterocycles tolerated</p>	
64		Arylation	ArBr		<p>Substrate (0.3 mmol), ArBr (0.36 mmol), [RuCl₂(<i>p</i>-cymene)]₂ (5 mol%), PPh₃ (40 mol%), Na₂CO₃ (2 equiv), toluene (2 mL), 130 °C, 15 h.</p> <p>30 Examples; Yield: 43-96%</p> <p>R¹ = OMe, OAc, Ph, F, Me; thiophene, pyrrole, chinolin tolerated</p> <p>R² = NMe₂, OMe, Ph, Cl, COOMe, CF₃, C(O)Me; pyridine and thiophene tolerated</p> <p>PhCl and PhOTf also tolerated</p>	48
65		Arylation	ArI		<p>Substrate (0.9 mmol), ArI (1.8 equiv), AgOAc (1.8 equiv), 110 °C, 20 h, neat</p> <p>27 Examples; Yield: 22-91%</p> <p>R = Me, halogen, OMe, CF₃, COOEt, CN, NO₂, C(O)Me, CHO, CH₂OH</p> <p>pyridine and thiophene tolerated</p> <p><i>cis</i>-selective</p>	108

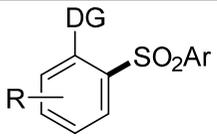
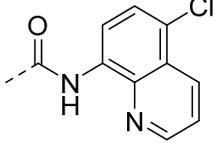
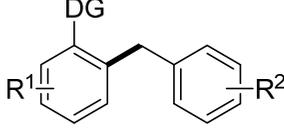
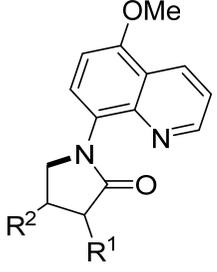
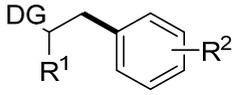
66		Arylation	ArI		<p>Substrate (0.2 mmol), ArI (1.0 mmol), Pd(OAc)₂ (10 mol%), AgOAc (0.4 mmol), (BnO)₂PO₂H (0.04 mmol), toluene (2 mL), 110 °C, 24 h.</p> <p>26 Examples; Yield: 26-93%</p> <p>R = Alkyl, halogen, CF₃, CN, COOMe, NO₂, OMe</p> <p>thiophene and pyridine tolerated</p>	109
67		Arylation	ArI		<p>Amide (0.3 mmol), ArI (0.6 mmol), Ni(OTf)₂ (0.1 equiv), MesCOOH (0.2 equiv), Na₂CO₃ (2 equiv), DMF (0.6 mL), 140 °C, 24 h</p> <p>21 Examples; Yield: 29-83%</p> <p>R¹–R² = Alkyl, Bn, Ph</p> <p>R³ = CF₃, COOMe, Ac, I, Cl, Me, NH₂, N(Me)₂, OMe, Me, indole and thiophene tolerated</p>	110
68		Arylation	ArI		<p>(±)-Substrate (0.25 mmol), ArI (4 equiv), Pd(OAc)₂ (5 mol%), AgOAc (2.2 equiv), toluene (3 mL), 110 °C, 24h.</p> <p>20 Examples, Yield: 40-93%; dr: 52:48 – 86:14</p> <p>R = Ph, H, COOEt, ^tBu</p> <p>good diastereoselectivity only if R = Ph</p>	111
69		Arylation	ArI		<p>8-Amino quinoline (0.3 mmol), benzoyl chloride (0.3 mmol), ArI (0.9 mmol), Pd(OAc)₂ (3 mol%), K₂CO₃ (0.6 mmol), xylene (2 mL), 120 °C, 12 h.</p> <p>28 Examples; Yield: 47-95%</p> <p>R¹ = Me, OMe, Cl</p> <p>R² = OMe, Me, C(O)Me, NO₂, Cl</p> <p>if R¹ is not in <i>meta</i>-position, monoarylation occurs</p> <p>DG introduction in-situ</p>	112

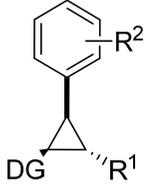
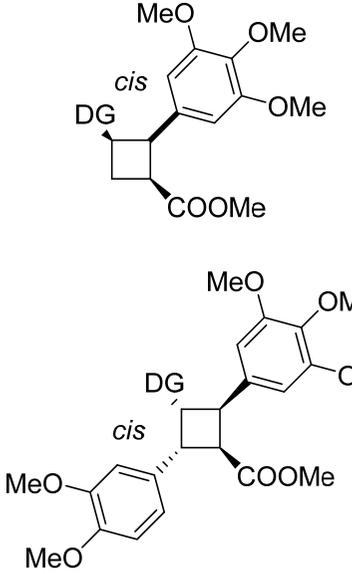
70		Arylation	PyrI		<p>Substrate (0.1 mmol), Pd(OAc)₂ (10 mol%), Ag₂CO₃ (1.5 equiv), NaI (30 mol%), (BuO)₂POOH (20 mol%), (toluene-DMA 20/1), 130 °C, 24 h</p> <p>27 Examples; Yield: 52-97%</p> <p>R¹ = Alkyl, aryl</p> <p>R² = Halogen, CF₃, CN, COOMe, OMe, Me, NHAc, NPr₂, NHPr</p>	113
71		Carbonylation (Intramolecular Cyclization)	DMF		<p>Substrate (0.2 mmol), NiBr₂ (10 mol%), Cu(acac)₂ (20 mol%), Na₂CO₃ (0.3 equiv), TBAPF₆ (1.5 equiv), O₂ (1 atm), DMF (5 mL), 160 °C, 24 h.</p> <p>R¹ = Alkyl, Ph, Bn, CF₃, COOEt</p> <p>R² = Alkyl</p> <p>n = 2-4</p> <p>The carbon atom in α-position to the initial carbonylation must be quaternary</p>	114
72		Carbonylation (Intramolecular Cyclization)	DMF		<p>Substrate (0.2 mmol), NiI₂ (10 mol%), Cu(acac)₂ (20 mol%), Li₂CO₃ (0.4 equiv), THAB (1 equiv), O₂ (1 atm), DMF (3.0 mL), 160 °C, 24 h.</p> <p>14 Examples; Yield: 51-90%</p> <p>R = OMe, Me, halogen, CF₃, NO₂</p>	114
73		Carbonylation (Intramolecular Cyclization)	CO		<p>Substrate (0.5 mmol), (Co(acac)₂ (20 mol%), NaOPiv (2 equiv), Mn(OAc)₃·2H₂O (1 equiv), CO (1 atm), CF₃CH₂OH (5 mL), rt, 16-60 h</p> <p>12 examples, 60-94% yield</p> <p>R = Me, CF₃, I, Br, NO₂, OMe, OCF₃, CN, COOEt</p>	115

74		Etherification	R ¹ OH		<p>R¹=Ar: Substrate (0.5 mmol), ArOH (0.5 mmol), Cu(OH)₂CO₃ (11 mol-%), K₂CO₃ (2 equiv), DMF, 110 °C, air.</p> <p>R¹= Alkyl: Substrate (0.5 mmol), ROH (5 equiv), Cu(OH)₂CO₃ (11 mol-%), TMG (2 equiv), pyridine, 110 °C, air.</p> <p>23 Examples; Yield: 39-85%</p> <p>R¹ = Aryl, alkyl</p> <p>R² = CF₃, NO₂, CN, OMe, Me</p> <p>pyridine tolerated</p>	116
75		Fluorination	AgF		<p>Monofluorination: Substrate (0.25 mmol), CuI (10–25 mol-%), AgF (3.5–4.0 equiv), NMO (4.5–5.0 equiv) in DMF (1 mL), 50–125 °C, 30–120 min.</p> <p>R = CF₃, COOMe, CN, OMe, F, Me</p> <p>pyridine tolerated</p> <p>Difluorination: Substrate (0.25 mmol), CuI (18 – 30 mol%), pyridine (2 equiv), AgF (5–6 equiv), NMO (7–8 equiv), DMF (1 mL), 75–105 °C, 1.5–2 h</p> <p>8 Examples; Yield: 61-77%</p> <p>R = CF₃, COOMe, CN, OMe, F, Me</p> <p>pyridine tolerated</p>	117
76		Nitration	NaNO ₂		<p>Mononitration: Substrate (0.3 mmol), NaNO₂ (0.9 mmol), Cu(OAc)₂·H₂O (0.6 mmol), K₂HPO₄ (0.6 mmol), MeOH (1 mL) air, 12 h</p> <p>19 Examples; Yield: 57-76%</p> <p>R = Alkyl, OMe, Ph, halogen, COOMe, CF₃</p> <p>heterocycles tolerated</p>	118

					<p>Dinitration: Substrate (0.3 mmol), NaNO₂ (0.9 mmol), Cu(OAc)₂·H₂O (0.6 mmol), AgOAc (0.6 mmol), DMF (1 mL), air, 12 h</p> <p>10 Examples; Yield: 47-63%</p> <p>R= Alkyl, OMe, F, COOMe</p> <p>pyridine tolerated</p>	
77		Phosphorylation			<p>Substrate (0.2 mmol), HPO(OR¹)₂ (2 equiv), Cu(OAc)₂ (20 mol%), NMO (2 equiv), Ag₂CO₃ (1 equiv), DMSO (0.8 mL), 4Å MS, 55 °C, 12h.</p> <p>24 examples, 36-78% yield</p> <p>R¹ = <i>i</i>-Pr, Et, <i>n</i>-Hex</p> <p>R² = Me, OMe, Halogen, CF₃, NO₂, CN, COOMe,</p> <p>pyridine, thiophene tolerated</p>	¹¹⁹
78		Silylation	<p>Me₃Si-SiMe₃ (or Me₃Ge- GeMe₃)</p>		<p>Substrate (0.2 mmol), Me₆Si₂ (1.0 mmol), Pd(OAc)₂ (10 mol%), Ag₂CO₃ (0.4 mmol), CaSO₄ (0.4 mmol), 1,4-dioxane (1.0 mL), 130 °C.</p> <p>17 examples, 28 – 82% yield</p> <p>R = Me, COOMe, OMe, OBn, OAc, C(O)Me, SO₃R, CF₃;</p> <p>thiophene, benzofuran tolerated</p>	¹²⁰
79		Sulfenylation	F ₃ CS-SCF ₃		<p>Substrate (1 equiv), CF₃S-SCF₃ (2–2.5 equiv), Cu(OAc)₂ (0.5 equiv), DMSO, 90–110 °C.</p> <p>10 examples, 43-76% yield</p> <p>R = <i>t</i>-Bu, Cl, OMe, Br, F, COOMe</p> <p>pyridine, thiophene tolerated</p>	¹²¹
80		Sulfenylation	ArS-SAr		<p>Substrate (1 mmol), diaryl disulfide (2 mmol), NiCl₂ (20 mol%), PPh₃ (20 mol%), Cs₂CO₃ (1 mmol), and dioxane (1 mL), 21 h, 140 °C</p>	¹²²

					7 examples, 36-98% yield R = OMe, Me, Cl	
81		Sulfenylation			Substrate (0.266 mmol), SF ₃ -source (0.2 mmol), Pd[CH ₃ CN] ₂ Cl ₂ (20 mol%), PivOH (10 equiv), DMF (2 mL), 70 °C, Ar. 22 examples, 8-53% yield R ¹ = Me, H R ² = Alkyl, Aryl	123
82		Sulfenylation	R ² SH		Substrate (0.2 mmol), thiol (2.5 equiv), Cu(OAc) ₂ ·H ₂ O (20 mol%), Ag ₂ CO ₃ (2 equiv), bathophen (40 mol%), NMP (2mL), 110 °C, 24-48 h, Ar. 30 examples, 16-93% yield R ¹ = Me, F, Br, CF ₃ , <i>t</i> -Bu, CN, NO ₂ , R ² = Alkyl, Aryl	124
83		Sulfenylation	RS-SR		Substrate (1 equiv), disulfide (2–2.5 equiv), Cu(OAc) ₂ (0.5 equiv), DMSO, 100–110 °C. 6 examples, 69-90% yield R = Ph, <i>i</i> -Pr, <i>t</i> -Bu, <i>n</i> -Bu, Bn, Aryl	121
84		Sulfonylation	ArSO ₂ Cl		Substrate (1.0 mmol), sulfonyl chloride (3.0 mmol), NiCl ₂ (50 mol%), Na ₂ CO ₃ (2.0 mmol), dioxan (1.0 mL), 24 h, 140 °C. 13 examples, 33-54 % yield R ¹ = Me, CF ₃ R ² = Me, F, CF ₃ , ^t Bu	122
85		Sulfonylation	ArSO ₂ Na		Substrate (0.3 mmol), sodium sulfinate (0.6 mmol), Cu(OAc) ₂ (0.3 mmol), K ₂ CO ₃ (0.6 mmol), DMF (1 mL), air, 4 h.	125

					<p>25 examples, 42-80 % yield</p> <p>R = OMe, Me, <i>t</i>-Bu, F, Cl, Br, CF₃, COOMe, NO₂</p> <p>Het = pyridine, thiophene</p>	
86		Sulfonylation	ArSO ₂ Cl		<p>Substrate (0.3mmol), arylsulfonyl chloride (0.36 mmol), PPh₃ (0.06 mmol), NaHCO₃ (0.6 mmol), Ni(OTf)₂ (0.03 mmol), toluene (2 mL) at 160 °C, 24h.</p> <p>11 examples, 21-85% yield</p> <p>R = Me, OMe, F, CF₃</p>	126
87		Benzylation	CH ₃ -Ar		<p>Substrate (0.3 mmol), Ni(OTf)₂ (0.03 mmol), PPh₃ (0.03 mmol), Na₂CO₃ (0.6 mmol), and ⁱC₃H₇I (0.6 mmol), toluene (1 mL), 140 °C, 24 h.</p> <p>28 Examples; Yield: 42-95%</p> <p>R¹ = Me, OMe, Cl, CF₃, C(O)Me, F,</p> <p>R² = CF₃, COOMe, Me, OMe, halogen, NHAc</p>	127
88		Amidation (Intramolecular)			<p>Substrate (0.2 mmol), Pd(OAc)₂ (5 mol%), PhI(OAc)₂ (2.5 equiv), toluene, 70-110 °C, Ar, 24 h.</p> <p>7 Examples, Yield: 59-87%</p> <p>R¹ = Me, ^tBuO</p> <p>R² = NHPht, H</p>	98
89		Arylation	ArI		<p>Substrate (1 equiv), ArI (3-4 equiv), Pd(OAc)₂ (0.05 equiv), CsOAc or K₂CO₃ (2.5 equiv), toluene, 90-110 °C</p> <p>7 Examples; Yield: 47-79%</p> <p>R¹ = Alkyl, OBn, phthalimide</p> <p>R² = Br, OCF₃, alkyl, Cl</p>	89

90		Arylation	ArI		<p>Substrate (0.25 mmol), ArI (1 mmol), Pd(OAc)₂ (5 mol%), AgOAc (0.55 mmol), toluene (2-3 mL), 110 °C, 12-24 h</p> <p>10 Examples; Yield: 40-88%</p> <p>R¹ = H, Ph</p> <p>R² = NO₂, OMe, alkyl, Ac; thipophene tolerated</p>	128
91		Arylation	ArI		<p>Substrate (1 equiv), ArI (2 equiv), Pd(OAc)₂ (0.15 equiv), Ag₂CO₃ (1.5 equiv), PivOH (1 equiv), HFIP, 90 °C, 36 h</p> <p>3 Examples; 46-81%</p> <p>applied in the total synthesis of piperarborenine B and D</p> <p>up to 20% diarylated byproduct</p> <p>gram scale</p>	129

Pyrimidine as directing group in C-H activation chemistry

Pyrimidine is after pyridine the second most frequently applied heterocyclic directing group. Typically, the 2-position of pyrimidine is connected to the substrate to be functionalized. If this attachment is via a C-C bond, pyrimidine is a permanent directing group and will remain in the final substrate. This of course is a drawback and limits the applicability to products which have pyrimidine as part of their structure. In case of a connection to a heteroatom, e.g. nitrogen, the pyrimidine DG can be cleaved using relatively simple conditions (e.g. NaOMe, DMSO, 100 °C). The more facile cleavage as compared to pyridine, where typically a twostep process of either reduction and hydrolysis or N-alkylation and hydrolysis is required, is due to the high electrophilicity of the C2 position due to electron withdrawal of 3 adjacent heteroatoms.

Palladium catalyzed acetoxylation and arylation was reported by the group of Chen (Table 3, Entry 1 & 27).³¹ In their case pyrimidine is linked via an oxygen to the system to be functionalized opening potential for DG cleavage, even though this has not been demonstrated. For arylation (Table 3, Entry 27) readily available arylboronic acids were used as coupling partners, whereas the acetoxylation (Table 3, Entry 1) relied on a hypervalent iodine reagent, namely PhI(OAc)₂. Both transformations showed a broad functional group tolerance.

Jiao and coworkers investigated the direct acylation (Table 3, Entry 2) and nitration (Table 3, Entry 38, 46) of arenes using series of directing groups including pyridine and pyrimidine.⁴⁰ For the nitration, *t*-butylnitrate (TBN) is the source of a NO₂ radical which is formed under aerobic conditions, giving overall a PdII/PdIV catalytic cycle. For the acylation, toluene serves as the source of a benzoyl radical in a twostep process. Initially, *N*-hydroxyphthalimide (NHPI) is converted under aerobic conditions to a phthalimido-*N*-oxyl (PINO) radical, which converts toluene to the benzoyl radical via single electron transfer (SET).

Alkenylation reactions of *N*-(2-pyrimidinyl)indole derivatives in position 2 of the indole ring have been reported with several different alkene sources (Table 3, Entries 3-8). The group of Ackermann applied alkenyl acetates (Table 3, Entry 5), alkenyl carbamates (Table 3, Entry 6), alkenyl phosphates (Table 3, Entry 7), and alkenyl carbonates (Table 3, Entry 8) under identical conditions.¹³⁰ Notable, the catalytic system consisted of the non-precious metal cobalt, which is of course highly desirable in metal catalysis. The simple salt CoI₂ in combination with a NHC ligand and either CyMgCl or DMPU as base promoted the desired transformation. More common are acrylates as reaction partners in alkenylations reactions.¹³¹ However, in such cases (e.g. Table entries 3&4) the substrate scope regarding the olefine is naturally limited.

Manganese catalyzed alkenylation of indole with alkynes was reported by Lei and Li (Table 3, Entries 9 & 26).²¹ As non-precious metal, manganese catalysis is especially attractive. In the specific example, depending on the reaction conditions, either the alkenylation product or annulation to carbazoles via twofold reaction with the alkyne component was observed. For both products also cleavage of the DG was demonstrated.

Alkylation reactions are a common transformation in C-H activation chemistry. The most frequently applied alkyl source are actually olefins and also for pyrimidine as DG such examples have been reported (Table 3, Entries 10, 12, 44).^{24, 132} An interesting alternative was published in 2015 by Jain and co-workers (Table 3, Entry 15). In their protocol, aliphatic carboxylic acids are used giving overall a decarboxylative alkylation reaction under palladium catalysis.¹³³ *N*-2-Pyrimidinylindolines were used as substrates

leading to alkylation in position 7. Examples with secondary and mainly tertiary carboxylic acids were reported. Decarboxylative arylation is typically more common and was applied to the C2 arylation of indole (Table 3, Entry 29).¹³⁴

Alkylation via ring opening of 2-vinyloxirane was reported under Rh catalysis by the group of Li (Table 3, Entry 14).²⁶ Yields were usually very high, often surpassing 90%. One drawback is the poor E/Z selectivity of the double bond in the products, which is often around 2:1, at best 6.1:1.

Meta selective alkylation has been reported by Ackermann and coworkers (Table 3, Entry 17).¹³⁵ Naturally, the pyrimidine DG mainly applied cannot reach out far enough to direct Ru insertion into the *meta* C-H bond. Indeed, “normal” *ortho* C-H insertion takes place. This leads to a metal complex in which the bond *para* to the Ru-C bond is weakened and prone to attack by a radical species formed from the tertiary alkyl bromides. This position *para* to the initially formed Ru-C bond is concomitantly *meta* to the position of the directing group, hence the observed meta alkylation. Detailed mechanistic studies have been carried out which support this mechanistic proposal.

A very comprehensive study on the alkynylation of various substrates has been reported by Xingwei Li and coworkers (Table 3, Entries 18-20).²⁸ They identified a catalytic system consisting of $[\text{RhCp}^*\text{Cl}_2]_2$ and $\text{Zn}(\text{OTf})_2$, hypervalent iodine-alkyne reagents which worked for the alkynylation of aromatics in combination with a series of heterocyclic DGs, including pyrimidine, pyridine and pyrrazole. Tuning the catalytic system allowed also the use of several other DGs such as *N*-methoxy imines, azomethine imines, secondary carboxamides, azo compounds, *N*-nitrosoamines, and nitrones (see corresponding sections).

Amides are important functional groups in organic chemistry and naturally the introduction of this functionality via C-H activation chemistry was investigated. Amidation reactions have been reported under rhodium catalysis using either isocyanates, *N*-hydroxycarbamates, or *N*-(2,4,6-trichlorobenzoyloxy)amides as amidating reagents (Table 3, Entries 21-25, 45). The latter one shows significant drawbacks regarding atom efficiency, which foils somehow the idea of C-H activation (Table 3, Entry 21).¹³⁶ Still, it gives very reliable results, only large amides such as pivaloylamide cannot be introduced via this method. Isocyanates are of course very reactive species and proved to be reliable amide precursors (Table 3, Entry 24).¹³⁷ It is worth mentioning that in a DG screening the usually very efficient 2-pyridyl group was significantly outperformed by the 2-pyrimidyl group. Most examples were carried out using aliphatic isocyanates, however also aromatic ones did work but with mediocre yields <50%.

Cyclopropenone ring opening towards chalcones was reported by the group of Li (Table 3, Entry 33).¹³⁸ With a single set of reaction conditions ($[\text{RhCp}^*\text{Cl}_2]_2$ and AgSbF_6) the transformation worked in combination with a series of directing groups including 2-pyrimidyl (others were 2-pyridyl, *N*-pyrazyl, and *N*-methoxy imine). These reaction conditions are quite common in C-H activation chemistry. The non coordinating anion SbF_6^- facilitates the formation of a cationic Rh-species which undergoes C-H insertion. Noteworthy, the authors were able to isolate several Rh(III) complexes and could show that they are part of the catalytic cycle. Hence, a mechanism was proposed strongly supported by experimental evidence.

Meta selective bromination by using NBS as brominating reagent was reported in a study focused on 2-aryl pyridines as substrates, but in three cases also pyrimidine was used as DG (Table 3, Entry 30).¹³⁹ The catalyst naturally inserts into the C-H bond *ortho* to the directing group. This activates the position *para* to this Ru-C bond for attack by a bromine radical generated from NBS. Hence, the meta bromination in respect to the DG.

Trifluoromethylallylation under Rh-catalysis was reported by Kim and coworkers³⁹ (Table 3, Entry 42).³⁹ The reaction was quite selective for the E-configuration of the resulting allyl group with E/Z selectivities ranging from 13:1 up to 35:1.

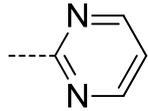
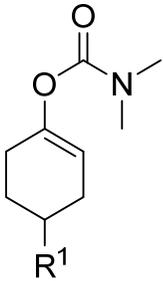
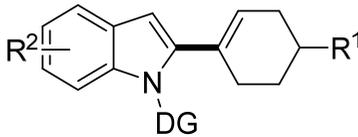
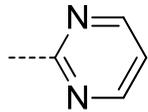
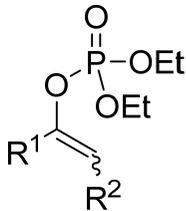
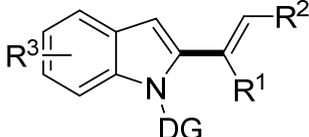
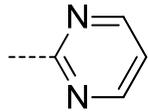
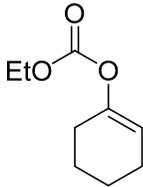
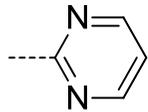
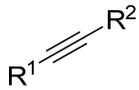
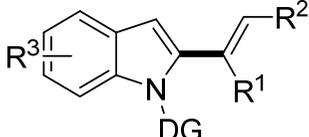
Cyanation in position 2 of indoles using *t*BuNC as the cyano source was reported by Xu and coworkers (Table 3, Entry 43, 47, 48).¹² The DG overrides the intrinsic reactivity of indoles, where the more electron rich 3-position would be preferentially cyanated in absence of a DG.

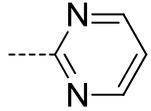
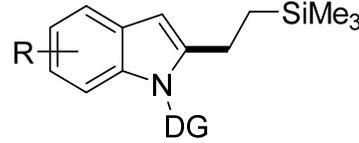
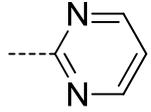
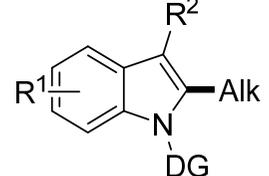
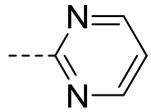
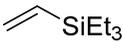
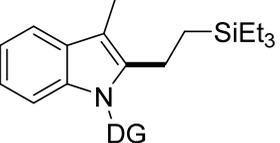
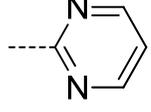
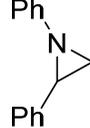
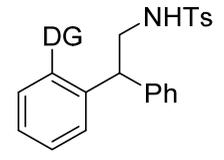
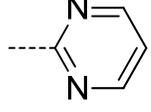
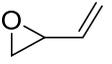
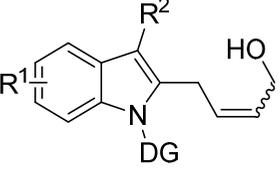
Cu-catalyzed oxidative coupling between indoles and benzoxazoles has been reported by Hirano and Miura (Table 3, Entry 34).¹⁴⁰ In this paper, they present a stoichiometric and a catalytic variant of this transformation, the latter one using air as terminal oxidant. Also removal of the DG was reported under standard conditions for cleaving *N*-linked 2-pyrimidyl groups. A second oxidative coupling method was reported as well, this time between indoles and *N*-oxides of 6-membered *N*-heterocycles (Table 3, Entry 35).¹³

A noteworthy example is also the indole synthesis reported by the group of Ackermann (Table 3, Entry 37).¹⁴¹ In this case *N*-2-pyrimidyl anilines are coupled to alkynes under Ni-catalysis, whereas the two carbons of the triple bond end up as C2 and C3 of the final indole products.

Table 3: Pyrimidine as directing group in C-H activation chemistry

Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
1		Acetoxylation	PhI(OAc) ₂		Substrate (1 equiv), PhI(OAc) ₂ (1.1 equiv), Pd(OAc) ₂ (2 mol%), AcOH/Ac ₂ O, 100 °C, 2-12 h; R ¹ = naphthyl, Cl, Me, COOMe, OMe. 17 examples, 24-87%	³¹
2		Acylation			Substrate (0.5 mmol), Pd(OAc) ₂ (10 mol%), NHPI (20 mol%), toluene (1 mL) at 80 °C under O ₂ (1 atm) for 24 h. Bis acylation was observed in several cases. 2 examples, R ¹ = H (62%), MeO (83%)	⁴⁰
3		Alkenylation			Substrate (0.25 mmol), alkene (0.30 mmol), [Cp*RhCl ₂] ₂ (5.0 mol%), and Cu(OAc) ₂ ·H ₂ O (1 equiv) in DCE under air at 60 °C for 5h. R ¹ = <i>n</i> Bu, <i>t</i> Bu, Me; R ² = H, Me, Br, I; R ³ = H, OMe, CN, Cl, F, NO ₂ , COOMe; 20 examples, (25-93% isolated yield) DG removed via NaOEt in DMSO, 100 °C.	¹³¹
4		Alkenylation			Substrate (0.25 mmol), Alkene (3 equiv), [Cp*RhCl ₂] ₂ (5.0 mol%), and Cu(OAc) ₂ ·H ₂ O (1 equiv) in DCE under air at 60 °C for 5 h. Single example, 75%; No reaction at rt.	¹³¹
5		Alkenylation			Substrate (0.50 mmol), acetate (0.75 mmol), CoI ₂ (10 mol%), ligand IPrHCl (10 mol%), CyMgCl (2.0 equiv), DMPU (1.5 mL), 23 °C, 16 h. R ¹ = <i>n</i> Pr, <i>n</i> Bu, Ph; R ² = Et, <i>n</i> Pr, Me; 4 examples, 50-80%	¹³⁰

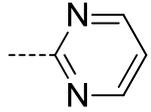
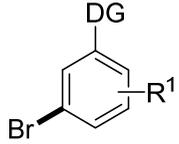
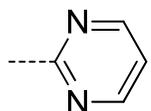
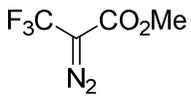
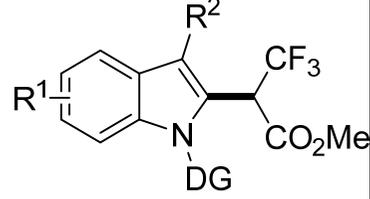
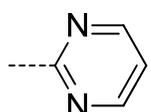
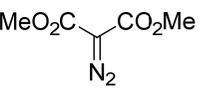
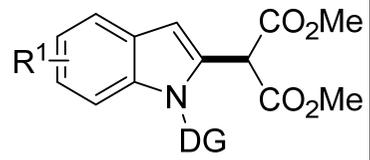
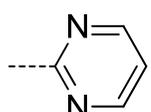
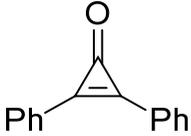
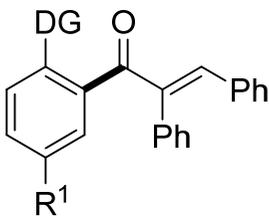
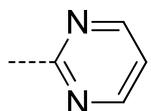
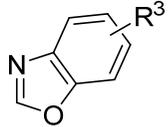
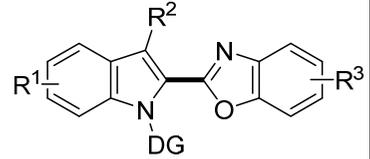
					Removal: NaOMe, DMSO 100 °C	
6		Alkenylation			Substrate (0.50 mmol), carbamate (0.75 mmol), CoI ₂ (10 mol%), ligand IPrHCl (10 mol%), CyMgCl (2.0 equiv), DMPU (1.5 mL), 23 °C, 16 h. R ¹ = H (87%), <i>n</i> Pent (82%), <i>On</i> Pent (79%); Removal: NaOMe, DMSO 100 °C	¹³⁰
7		Alkenylation			Substrate (0.50 mmol), phosphate (0.75 mmol), CoI ₂ (10 mol%), ligand IPrHCl (10 mol%), CyMgCl (2.0 equiv), DMPU (1.5 mL), 23 °C, 16 h. R ¹ = <i>n</i> Pr, <i>n</i> Bu, Ph; R ² = Et, <i>n</i> Pr, Me; R ³ = H, OEt, F; Also cyclohexene-phosphates were used successfully 11 examples, 50-83% Removal: NaOMe, DMSO 100 °C	¹³⁰
8		Alkenylation			Substrate (0.50 mmol), carbonate (0.75 mmol), CoI ₂ (10 mol%), ligand IPrHCl (10 mol%), CyMgCl (2.0 equiv), DMPU (1.5 mL), 23 °C, 16 h. Single example, 56%	¹³⁰
9		Alkenylation			Substrate (1 equiv), alkyne (1.5 equiv), MnBr(CO) ₅ (10 mol%), DIPEA (20 mol%), PhCOOH (20 mol%), Et ₂ O, 80 °C, Ar, 12 h. R ¹ = H, Me, Ph, COOEt, 2-thienyl, 4-tolyl; R ² = aryl, COOEt, 2-thienyl; R ³ = H, F, Cl, Br, Me, MeO; 24 examples, 17-98%. DG removal: NAOMe (5 equiv), DMSO, 110 °C, 24 h, 1 example, 62%.	²¹

					Pyrrole as substrate gives bis-alkenylation ($R^{1,2} = \text{Ph}$, 41%).	
10		Alkylation			Substrate (5.0 mmol), vinylsilane (1.5 equiv), CoBr_2 (10 mol-%), bathocup (10 mol-%), CyMgBr (60 mol-%) in THF (2 mL) at 60 °C for 12 h. R = H, F, Cl, MeO, Me, Et; other vinylsilanes applied: $\text{CH}_2=\text{CHSiPh}_3$ and $\text{CH}_2=\text{CHSiMe}_2\text{Ph}$; 11 examples, 30-80% Reaction also in gram scale reported. Removal: NaOEt in DMSO, 100 °C, 12h.	132
11		Alkylation	Alk-Cl		Substrate (1 equiv), Alk-Cl (1.2 equiv), $\text{Co}(\text{acac})_2$ (10 mol%), IPrHCl (20 mol%), CyMgCl , DMPU, 23 °C, 16 h. $R^1 = \text{H, Et}$; Alk = <i>n</i> Hex, <i>n</i> Oct, $(\text{CH}_2)_3\text{Ph}$; 4 examples, 71-86%.	16
12		Alkylation			Substrate (1 equiv), alkene (3 equiv), $[\text{RuCl}_2(\text{p-cymene})]_2$ (2.5 - 5 mol%), MesCOOK (30 mol%), toluene, 100 - 120 °C, 18 - 24 h. Single example, 83%.	24
13		Alkylation via aziridine opening			Substrate (1 equiv), aziridine (2 equiv), $[\text{Cp}^*\text{RhCl}_2]_2$ (5 mol%), AgSbF_6 (30 mol%), PhCl, 100 °C, 20 h. The reaction was developed for 2-arylpyridine derivatives (21 examples, 48-90%) Single example with pyrimidine as DG, 63%	25
14		Alkylation			Substrate (1 equiv), 2-vinylloxirane (1.2 equiv), PivOH (1 equiv), $[\text{Cp}^*\text{Rh}(\text{MeCN})_3]\text{SbF}_6$ (3 mol%), Ar, 25 °C, 16 h $R^1 = \text{H, Me, Et, OBn, OMe, Br, Cl, COOMe}$; $R^2 = \text{H, Me, CH}_2\text{CH}(\text{NHBoc})(\text{COOMe})$; 17 examples, 59-97% (E/Z = 1.5 : 1 - 6.1 : 1)	26

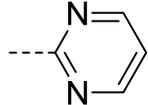
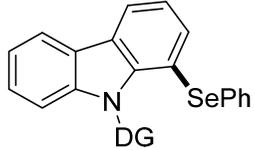
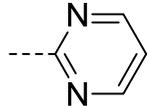
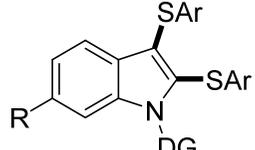
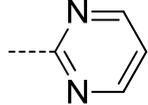
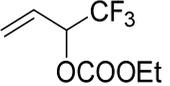
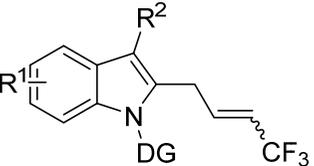
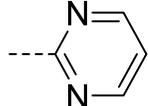
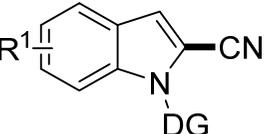
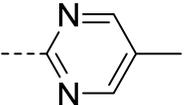
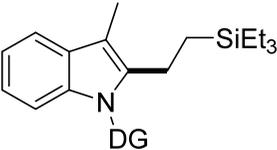
15		Alkylation	RCOOH		Substrate (1.0 equiv), reagent (2.0 equiv), $\text{PhI}(\text{OAc})_2$ (2.0 equiv), $\text{Pd}(\text{OAc})_2$ (10 mol%), 40 °C, 2 h. R = secondary and tertiary alkyls; 10 examples, 73-92%. Inhibited by ascorbic acid.	133
16		Alkylation	$\text{R}^1\text{-BF}_3\text{K}$		Substrate (1 equiv), $\text{R}^1\text{-BF}_3\text{K}$ (3 equiv), AgF (2.8 - 4 equiv), $[\text{Cp}^*\text{RhCl}_2]_2$ (4 mol%), AgSbF_6 (16 mol%), DCE, 100 °C, 24 h. $\text{R}^1 = \text{Me}, n\text{Bu}$; $\text{R}^2 = \text{H}, \text{Me}$; $\text{R}^3 = \text{H}, \text{OBn}, \text{MeO}, \text{Cl}, \text{Et}$; 7 examples, 42-91%. Many other DGs successfully applied in this contribution	11
17		Alkylation			Substrate (1 equiv), alkyl bromide (3 equiv), $[\text{RuCl}_2(\text{p-cymene})]_2$ (5 mol%), Piv-Val-OH (30 mol%), K_2CO_3 , 1,4-dioxane, 120 °C, 16 h. $\text{R}^1 = \text{H}, \text{OMe}, \text{Br}, \text{Cl}, \text{F}$; $\text{R}^2 - \text{R}^4 = \text{various alkyl species}$; 14 examples, 40-66%.	135
18		Alkynylation			Substrate (0.2 mmol), R-EBX (0.22 mmol), $[\text{RhCp}^*\text{Cl}_2]_2$ (2 mol%), $\text{Zn}(\text{OTf})_2$ (0.02 mmol, 10 mol%), DCE (2 mL), 25 or 80 °C, 16 h $\text{R}^1 = \text{TIPS}, \text{TES}$; $\text{R}^2 = 2\text{-Me}, 2\text{-Cl}, 2\text{-CF}_3, 4\text{-CF}_3$; 4 examples, 50-91% Also thiophene can be selectively mono-alkynylated (80%)	28
19		Alkynylation			Substrate (0.2 mmol), R-EBX (0.22 mmol), $[\text{RhCp}^*\text{Cl}_2]_2$ (2 mol%), $\text{Zn}(\text{OTf})_2$ (0.02 mmol, 10 mol%), DCE (2 mL), 25 or 80 °C, 16 h $\text{R}^1 = \text{TIPS}, \text{TES}, t\text{Bu}$; $\text{R}^2 = \text{H}, \text{Me}$; $\text{R}^3 = \text{H}, \text{OBn}, \text{MeO}, \text{Cl}$; 5 examples, 85-92% DG cleavage: NaOEt, DMSO	28

20		Alkynylation			Substrate (0.2 mmol), R-EBX (0.46 mmol), [RhCp*Cl ₂] ₂ (2 mol%), Zn(OTf) ₂ (0.02 mmol, 10 mol%), DCE (2 mL), 25 °C, 16 h R = TIPS (89%), single example	28
21		Amidation			Substrate (0.20 mmol), acetamide (0.24 mmol), [Cp*Rh(MeCN) ₃](SbF ₆) ₂ (5 mol%), DCE (1 mL), 80 °C, 5-12 h. - No reaction for R ¹ = t-Bu because of steric hindrance. - DG was removable with EtONa in DMSO, 100 °C. R ¹ = Me, <i>i</i> Pr, Bn, Ph, <i>O</i> tBu, <i>t</i> Bu; R ² = H, MeO, CN, Br, F, Cl, NO ₂ , COOMe, Me, CONHBn; 24 examples, 54-85%	136
22		Amidation	HO-NH-Cbz		Substrate (1 equiv), <i>N</i> -Hydroxycarbamate (1.2 equiv), [RhCp*(CH ₃ CN) ₃](SbF ₆) ₂ (2.5 mol%), Ag ₂ CO ₃ (1.5 equiv), THF, 100 °C, 10 h, under air. 2 examples, R ¹ = H (60%), Me (64%)	142
23		Amidation			Substrate (1 equiv), phthalimide (1.2 equiv), CuOAc (20 mol%), toluene/ <i>o</i> -dichlorobenzene (1:1), 150 °C, O ₂ , 2-3 days. R ¹ = H, Me; R ² = H, Me, MeO, F, Cl, Br, CN; 8 examples, 31-86% (NO ₂ was not tolerated)	29
24		Amidation	R-NCO		Substrate (1 equiv), isocyanate (3 equiv), [RhCp*Cl ₂] ₂ (2 mol%), AgSbF ₆ (20 mol %), DCE, 100 °C, 24 h R ¹ = Et, <i>n</i> Bu, <i>n</i> Pent, <i>n</i> Hex, <i>n</i> Oct, Bn, CH ₂ CH ₂ Ph, cyclopentyl, Ar; R ² = H, OMe, NO ₂ , Br, Cl, F, Me;	137

					Also pyrrole and tetrahydroindole are potential substrates. 24 examples, 26-94%	
25		Amidation			Substrate (1 equiv), dioxazolone (1.2 equiv), Cp*Co(CO)I ₂ (2.5 - 5 mol%), AgSbF ₆ (5 - 10 mol%), NaOAc (5- 10 mol%), DCE, 70-100 °C, 20 h. R ¹ = H (94%), Me (65%).	15
26		Annulation			Substrate (1 equiv), alkyne (2.5 equiv), MnBr(CO) ₅ (20 mol%), DIPEA (40 mol%), Et ₂ O, 80 °C, Ar, 12 h. R ¹ = H, 6-Me, 6-Br; R ² = Ph, 4-tolyl, 2-thienyl; 5 examples, 14-29% DG removal: NaOMe (5 equiv), DMSO, 110 °C, 24 h, 1 example, 65%.	21
27		Arylation	Ar-B(OH) ₂		Substrate (1 equiv), Ar-B(OH) ₂ (2 equiv), Pd(OAc) ₂ (5 mol%), Cu(OTf) ₂ (1 equiv), Ag ₂ O (1 equiv), toluene, 120 °C, 24 h; R ¹ = naphthyl, Cl, Me, COOMe, CHO; Ar = Ph, 2-MeC ₆ H ₄ , 3-MeC ₆ H ₄ , 4-MeC ₆ H ₄ , 4-ClC ₆ H ₄ , 4-CF ₃ C ₆ H ₄ ; 18 examples, 17-75%	31
28		Arylation			Substrate (1 equiv), dienone (1.2. equiv), [Cp*RhCl ₂] ₂ (5 mol%), AgSbF ₆ (30 mol%), Zn(NTf ₂) ₂ (20 mol%), DCE, 100 °C, 20h Single example, 45%	35
29		Arylation	Ar-COOH		- Substrate (0.5 mmol), ArCOOH (0.75 mmol), [Rh(CO) ₂ Cl] ₂ (2.5 mol%), (tBuCO) ₂ O (0.75 mmol), toluene (3.0 mL), 140 °C, 12 h. 37 examples, 72-96% isolated yield	134

30		Bromination	NBS		Substrate (1 equiv), NBS (2 equiv), [RuCl ₂ (p-cymene)] ₂ (5 mol%), DMA, 80 °C, 24 h. R ¹ = H, Me; 3 examples, 84-90%.	139
31		Carbenoid insertion	 CF ₃ -carbenoid		Substrate (0.2 mmol), reagent (0.24 mmol), [Cp* ⁺ RhCl ₂] ₂ (2 mol-%), AgSbF ₆ (10 mol-%), DCE (2 mL), 80 °C, 4h. R ¹ = H, NO ₂ , COOMe; R ² = Me, COOMe; 5 examples, 68-92%	143
32		Carbenoid insertion			Substrate (1 equiv), diazo reagent (1.2 equiv), Cp* ⁺ Co(CO)I ₂ (5 mol-%), AgSbF ₆ (10 mol-%), DCE, 10 °C, 20-48 h. Pyrrole can be used as substrate as well. R ¹ = H, OMe, Br, OBn, COOMe, CHO, NO ₂ , Cl; 14 examples, 24-85%	144
33		Cyclopropanone ring opening			2-Arylpyrimidine (0.24 mmol), cyclopropanone (0.2 mmol), [RhCp*Cl ₂] ₂ (2.5 mol%), AgSbF ₆ (15 mol%), DCM (3 mL), 60 °C, 20 h, sealed tube under argon. R ¹ = H (82%), Me (85%), COMe (78%); Instead of phenyl 2-thienyl can be functionalized as well (89%).	138
34		Heteroarylation			Substrate (1 equiv), oxazole (2 equiv), Cu(OAc) ₂ (20 mol%), AcOH (4 equiv), o-xylene, 150 °C, air, 4-6 h. R ¹ = H, 3-Cl; R ² = H, CN, Cl; R ³ = H, NO ₂ , Me; Besides benzoxazoles also 5-aryloxazoles were used as coupling partner; In one case 2-ethylpyrrole was used as substrate; 11 examples, 42-81% DG cleavage: NaOMe, DMSO, 100 °C (4 examples, 56-88%).	140

35		Heteroarylation			<p>Indole or pyrrole substrate (1 equiv), N-oxide (4 equiv), Pd(OAc)₂ (10-20 mol%), DPPB (10-20 mol%), Cu(OAc)H₂O (3 equiv), pyridine (2 equiv), 1,4-dioxane, 140 °C, 30 h.</p> <p>Indoles (eventually carrying BnO, MeO) and pyrrole was used as substrate; N-oxides of quinoline, quinoxaline, and pyridine were used; 6 examples, 50-71%</p> <p>DG was cleaved (NaOEt, DMSO, 120 °C) without compromising the N-oxide.</p>	13
36		Imine addition			<p>Substrate (1 equiv), imine (1.08 equiv), [Cp*Rh(CH₃CN)₃]SbF₆ (5 mol%), <i>t</i>AmylOH, 85 °C, 16 h; Single example, 74%</p>	37
37		Indole synthesis			<p>Substrate (1 equiv), alkyne (3 equiv), Ni(cod)₂ (10 mol%), dppf (20 mol%), neat, 160 °C, 20 h.</p> <p>R¹ = H, Me, MeO, CF₃, Ph, CN, F, Cl; R² = aryl; R³ = aryl or <i>t</i>Bu;</p> <p>20 examples, 55-90%</p> <p>If R¹ = 3-F a mixture of 2 regioisomers was isolated.</p>	141
38		Nitration			<p>- Substrate (0.3 mmol), Pd(OAc)₂ (10 mol%), TBN (2.0 equiv), PhCl (1 mL), at 80 °C under O₂ (1 atm) for 24 h.</p> <p>R¹ = 2-Me, 3-Me, 3-MeO; 3 examples, 55-79%</p>	40
39		Selenylation	PhSeSePh		<p>Substrate (1 equiv), PhSeSePh (1 equiv), Pd(OAc)₂ (10 mol%), CuBr₂ (2 equiv), DMF, 80 °C, 48 h.</p> <p>Single example, 67%</p>	38

40		Selenylation	PhSeSePh		Substrate (1 equiv), PhSeSePh (1 equiv), Pd(OAc) ₂ (10 mol%), CuBr ₂ (2 equiv), DMF, 80 °C, 48 h. Single example, 98%	38
41		Sulfenylation	ArSSAr		Substrate (1 equiv), ArSSAr (1 equiv), Pd(OAc) ₂ (10 mol%), CuBr ₂ (2 equiv), DMF, 140 °C, 24 h. R = H, Cl; Ar = Ph, 2,5-Cl ₂ C ₆ H ₃ ; 3 examples 61-69%. For Ar = 4-MeOC ₆ H ₄ mono-sulfenylation in position 2 took place; If C3 of indole was blocked by a Me group only C2 sulfenylation took place in 94%.	38
42		Trifluoromethyl-allylation			Substrate (1 equiv), alkene (2 equiv), [Cp*RhCl ₂] ₂ (2.5 mol%), AgSbF ₆ (10 mol%), Cu(OAc) ₂ (50 mol%), THF, air, 120 °C, 24 h R ¹ = H, OMe, Br, Cl, NO ₂ , Me, F; R ² = H, Me, COOMe; 16 examples 66% (16:1 E/Z) Pyrrole is also a substrate for this transformation.	39
43		Cyanation	<i>t</i> BuNC		Substrate (1 equiv), <i>t</i> BuNC (3 equiv), Pd(OAc) ₂ (5 mol%), Cu(TFA) ₂ (3 equiv), DMF, O ₂ , 130 °C R ¹ H, OMe, COOMe, Br, Me; 7 examples, 33-92% In absence of a DG cyanation takes place in position 3 of indole.	12
44		Alkylation			Substrate (1 equiv), alkene (3 equiv), [RuCl ₂ (<i>p</i> -cymene)] ₂ (2.5 - 5 mol%), MesCOOK (30 mol%), toluene, 100 - 120 °C, 18 - 24 h. Single example, 74%.	24

45		Amidation			Substrate (1 equiv), phthalimide (1.2 equiv), CuOAc (20 mol%), toluene/o-dichlorobenzene (1:1), 150 °C, O ₂ , 2-3 days. Single example, 77% (NO ₂ was not tolerated)	²⁹
46		Nitration			Substrate (0.3 mmol), Pd(OAc) ₂ (10 mol%), TBN (2.0 equiv), PhCl (1 mL), at 80 °C under O ₂ (1 atm) for 24 h. Single example, 78%	⁴⁰
47		Cyanation	<i>t</i> BuNC		Substrate (1 equiv), <i>t</i> BuNC (3 equiv), Pd(OAc) ₂ (5 mol%), Cu(TFA) ₂ (3 equiv), DMF, O ₂ , 130 °C Single examples, 83% In absence of a DG cyanation takes place in position 3 of indole.	¹²
48		Cyanation	<i>t</i> BuNC		Substrate (1 equiv), <i>t</i> BuNC (3 equiv), Pd(OAc) ₂ (5 mol%), Cu(TFA) ₂ (3 equiv), DMF, O ₂ , 130 °C Single examples, 85% In absence of a DG cyanation takes place in position 3 of indole.	¹²

Pyrazole derivatives in C-H activation chemistry

Studies which focus on the application of pyrazole as directing group are reaction quite rare. It is much more common that a method is developed for another directing group and then a few examples are given in substrate scope tables showing that also other directing groups can be reacted under certain reaction conditions. It is amongst these “other directing groups” where pyrazole typically finds its place. Hence, the examples given in certain studies are typically only few, which can be seen in the table. Most of the reports have already been discussed in other sections, and hence, here only studies will be discussed in more detail, which have not been discussed elsewhere and in which pyrazole really plays a prominent role.

First of all, in comparison to electron poor heterocycles, pyrazole can be directly functionalized itself under e.g. palladium catalysis^{145, 146} and this is a potential side reaction which has to be considered when pyrazole shall be used as DG. Either substituted pyrazoles have to be used which cannot undergo C-H activation anymore, or catalytic systems unable to activate a pyrazole C-H bond have to be found. Hence, typical conditions use Rh, Ru, or Ir but not Pd. Palladium becomes an option when pyrazole cannot be activated, or when this is a desired step, as it is the case in the intramolecular reaction given in Table 4, Entry 20.¹⁴⁷ Here, the reaction consists of actually three C-H activation steps, in which the first one is a pyrazole directed arylation of a C(sp³)-H bond of the t-butyl group in position 3 of the pyrazole ring, according to the proposed mechanism. Intramolecular oxidative coupling of the arylated intermediate with position 4 of the pyrazole DG leads to the tricyclic products depicted in entry 5. In this pyrazole activation step, the amide group in position 5 acts as the directing group, so the pyrazole substrate can be considered as a directing group carrying directing group in this specific very elegant cascade of C-H activation steps.

Alkenylations using a Rh or Ru catalyst, an alkyne as coupling partner (leading to alkenes via a hydroarylation pathway), an additive with a non-coordinating anion (e.g. AgSbF₆) and a carboxylic acid are quite common and have been reported on a number of occasions. Also *N*-phenylpyrazole was used in such a transformation giving high yields in all prepared examples (Table 4, Entry 1).¹⁴⁸ The alkynes applied were however limited to substituted 1,2-diphenylacetylenes in most cases. When 1-phenyl-1-propyne was used as coupling partner, the new C-C bond was predominantly formed to the C2 position of the alkyne and only minor amounts of isomers were detected.

Phosphoramidation using diphenyl phosphorazidate as coupling partner was reported under iridium catalysis (Table 4, Entry 16).¹⁴⁹ In five examples pyrazole was the DG (typically 2-pyridyl was used) and in all examples yields between 60-69% were obtained. Also in this case it can be expected that a cationic metal complex plays a key role since [IrCp*Cl₂]₂ in combination with AgSbF₆ was used. Phosphoramidates are reoccurring motifs in pharmaceuticals making this method interesting for medicinal chemistry applications.

Carbenoid C-H functionalization is an area which has gained some prominence in the last year. Huw Davies pioneered the reaction of a series of saturated carbocyclic and heterocyclic substrate using a chiral Rh catalyst, leading to high ees in most cases.¹⁵⁰⁻¹⁵² These transformations did not require a DG. Directed carbenoid insertion was then first reported by Yu.¹⁵³ Using pyrazole as directing group, Osipov and coworkers developed a pyrazole directed protocol (Table 4, Entry 22) which was then expanded to other DGs (ketone methoximes, pyrimidines) in the same contribution.¹⁴³ Typical for this type of reactions is the necessity of two electron withdrawing substituents on the

diazo compound, CF_3 and COOMe in the present case. In the same year also a Co-catalyzed carbenoid insertion was published using diazo malonates as coupling partners (Table 4, Entry 11).¹⁴⁴

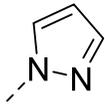
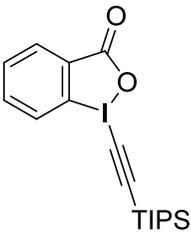
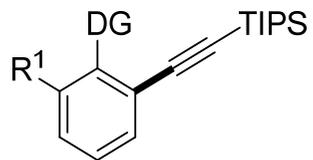
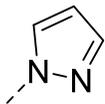
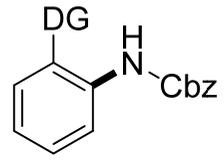
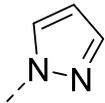
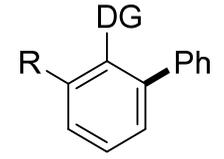
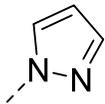
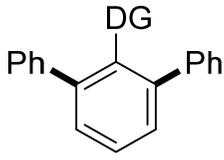
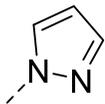
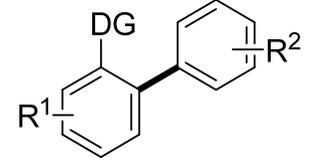
One of the earliest examples using pyrazole as DG was reported by Chatani and coworkers (Table 4, Entry 12).¹⁵⁴ They used *N*-phenylpyrazole as substrate and developed a carbonylation protocol under neutral conditions using $\text{Ru}_3(\text{CO})_{12}$ as catalyst, of CO and ethylene at pressures of 20 atmospheres. Electron donating substituents on the phenyl ring gave significantly better yields than electron withdrawing ones. Also electron rich thiophene could be carbonylated in a reasonable yield of 54%.

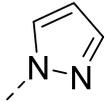
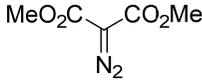
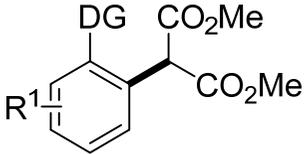
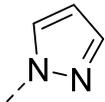
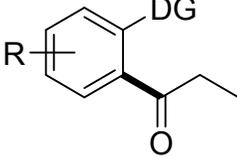
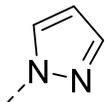
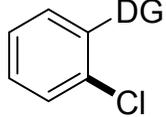
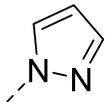
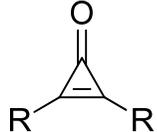
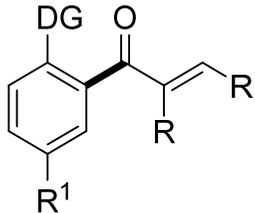
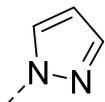
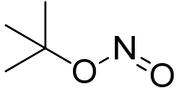
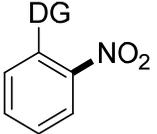
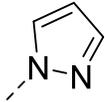
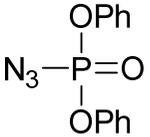
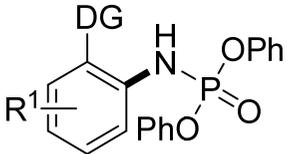
Oro and Castarlenas reported the coupling of *N*-vinylpyrazoles with alkynes to give Markovnikov selective butadienylpyrazole derivatives (Table 4, Entry 23).¹⁵⁵ A rhodium catalyst carrying an NHC ligand proved to be most effective and the reaction worked at relatively mild temperatures of 70 °C. The proposed mechanism, which was supported by isolation of some intermediate Rh-complexes of the catalytic cycle, starts with precoordination of Rh to pyrazole and subsequent activation of the vinyl substituent. Subsequent alkyne coordination, hydrometallation and reductive elimination delivered the target products.

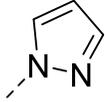
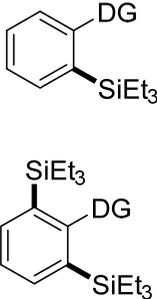
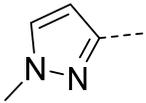
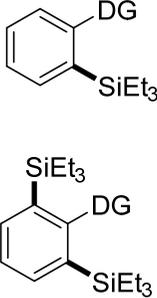
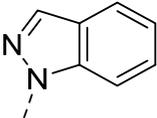
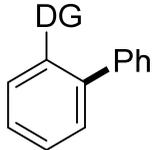
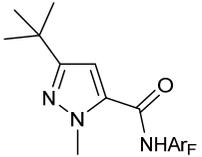
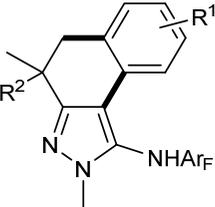
Miao and Zhang delivered a report in which a pyrazolone directing group played a dual role (Table 4, Entry 24).¹⁵⁶ First, it precoordinated a Rh catalyst allowing C-H insertion in ortho position of the attached phenyl ring. According to the suggested mechanism, the pyrazole N-N bond of the directing group is cleaved, one nitrogen ending up in the indole ring of the final product (red nitrogen Table entry), the other forming the amino group on the side chain. Huang and coworkers reported a similar transformation but using a differently substituted DG as starting material which also leads to differently substituted indole products (Table 4, Entry 25).⁷⁸

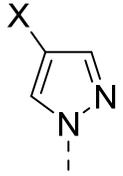
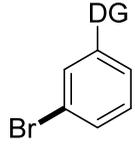
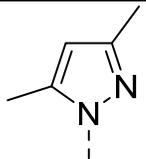
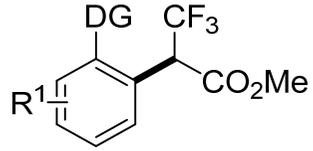
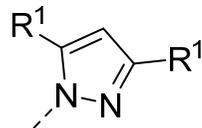
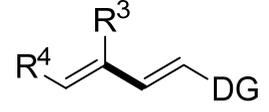
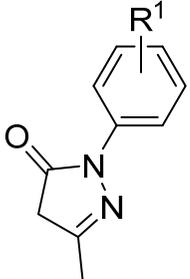
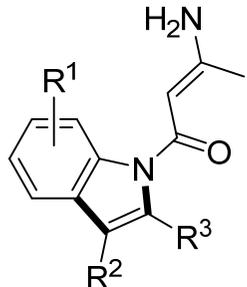
Table 4: Pyrazole as directing group in C-H activation reactions

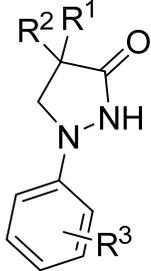
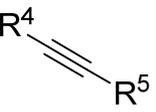
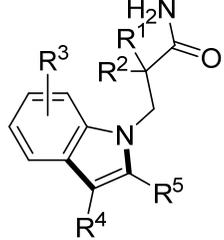
Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
1		Alkenylation			Substrate (1 equiv), alkyne (2.5 equiv), [RuCl ₂ (<i>p</i> -cymene)] ₂ (5 mol%), AgSbF ₆ (20 mol%), AcOH (4 equiv), 1,4- dioxane, 100 °C, 5 h, N ₂ R ¹ = H, CH ₃ , MeO, Cl; R ² = aryl, alkyl; R ³ = aryl 8 examples, 77-89% Amide DGs can enable mono olefination with the same catalytic system	¹⁴⁸
2		Alkylation			Substrate (1 equiv), alkene (3 equiv), [RuCl ₂ (<i>p</i> -cymene)] ₂ (2.5 - 5 mol%), MesCOOK (30 mol%), toluene, 100 – 120 °C, 18 – 24 h. Single example, 65%	²⁴
3		Alkylation via aziridine opening			Substrate (1 equiv), aziridine (2 equiv), [Cp* <i>Rh</i> Cl ₂] ₂ (5 mol%), AgSbF ₆ (30 mol%), PhCl, 100 °C, 20 h. The reaction was developed for 2-arylpyridine derivatives (21 examples, 48-90%) Single example with pyrazole, 58%	²⁵
4		Alkylation			Substrate (1 equiv), 2-vinyloxirane (1.2 equiv), PivOH (1 equiv), [Cp* <i>Rh</i> (MeCN) ₃][SbF ₆] (3 mol%), Ar, 25 °C, 16 h Single example, 75% (E/Z = 4.9 : 1)	²⁶
5		Alkylation			Substrate (1 equiv), olefine (2 equiv), [RuCl ₂ (<i>p</i> -cymene)] ₂ (1 mol%), O ₂ (1 atm), toluene, 120 °C. The reaction was developed for 2-arylpyridine derivatives (14 examples, 40-94%) Single example on indole, 72%.	²⁷

6		Alkynylation			<p>Substrate (0.2 mmol), R-EBX (0.22 mmol for mono-alkenylation, 0.46 mmol for bis-alkenylation), [RhCp*Cl₂]₂ (2 mol%), Zn(OTf)₂ (0.02 mmol, 10 mol%), DCE (2 mL), 25 °C, 16 h;</p> <p>One example for mono-alkenylation (R¹ = CH₃ in the substrate, 78%) and one for bis-alkenylation (R¹ = H in the substrate, 91%)</p>	28
7		Amidation	HO-NH-Cbz		<p>Substrate (1 equiv), OH-carbamate (1.2 equiv), [RhCp*(CH₃CN)₃](SbF₆)₂ (2.5 mol%), Ag₂CO₃ (1.5 equiv), THF, 100 °C, 10h, under air.</p> <p>Single example, 46 %</p>	142
8		Arylation	Ar-Br		<p>Substrate (0.5 mmol), PhBr (0.6 mmol), [RuCl₂(η⁶-C₆H₆)₂] (0.0125 mmol), PPh₃ (0.05 mmol), K₂CO₃ (1.0 - 2.0 mmol), NMP (1 mL), 120 °C, N₂, 20 h.</p> <p>R = Me, 1 example, 92%, R = H: bisarylation occurred (R = Ph), 97%.</p>	157
9		Arylation	Ph-Cl		<p>Phenylpyridine (0.5 mmol), chlorobenzene (1.25 mmol, 2.5 equiv), [RuCl₂(<i>p</i>-cymene)]₂ (2.5 mol%), KO^tPiv (10 mol%), K₂CO₃, (3 equiv), DEC (2 mL), 120 °C and 10 h or 80 °C and 24 h</p> <p>Single example, 91%</p>	158
10		Arylation	Ar-B(OH) ₂		<p>Substrate (1 equiv), boronic acid (1.2 equiv), [RuCl₂(<i>p</i>-cymene)]₂ (2.5 mol%), PhI(OCOCF₃)₂ (20 mol%), toluene, 100 °C, 2 h.</p> <p>7 examples, 64-85%</p> <p>Main focus of the paper is the arylation of 2-arylpyridines.</p>	159

11		Carbenoid insertion			Substrate (1 equiv), reagent (1.2 equiv), Cp*Co(CO)I ₂ (5 mol-%), AgSbF ₆ (10 mol-%), DCE, 10 °C, 11-48 h. R ¹ = H, COMe, CN, CH ₂ OH, COOEt, Cl; DG can also be substituted (Me, COMe), 13 examples, 11-80%	144
12		Carbonylation	CO, CH ₂ =CH ₂		Substrate (2 mmol), ethylene (7 atm), CO (20 atm), Ru ₃ (CO) ₁₂ (0.05 mmol) in DMA (6 mL) at 160 °C for 20 h. 9 examples, 31-94%, R = 4-CH ₃ , 4-MeO, 4-CF ₃ , 3-MeO, 3-COOMe, 2-MeO, 2-naphtyl, 3-thienyl	154
13		Chlorination	NCS		Pd(OAc) ₂ (5 mol%), NCS (1.05 equiv), AcOH, 100 °C, 12 h. 1 example, 58%.	160
14		Cyclopropenone ring opening			2-phenylpyridine (0.24 mmol), cyclopropanone (0.2 mmol), [RhCp*Cl ₂] ₂ (2.5 mol%), AgSbF ₆ (15 mol%), DCM (3 mL), 60 °C, 20 h, sealed tube under argon. 2 examples, R ¹ = H (72%), COOMe (75%)	138
15		Nitration			Substrate (0.3 mmol), Pd(OAc) ₂ (10 mol%), TBN (2.0 equiv), PhCl (1 mL), at 80 °C under O ₂ (1 atm) for 24 h. Single example, 61%	40
16		Phosphoramidation			Substrate (0.1 mmol), 2 (0.2 mmol), [IrCp*Cl ₂] ₂ (4 mol%), AgSbF ₆ (16 mol%), AgOAc (50 mol%) and DCM (1.0 mL) under Ar, 24 h, 60 °C. R ¹ = Me, MeO, Cl; 5 examples, 60 - 69%	149

17		Silylation	HSiEt ₃		<p>Substrate (1 mmol), HSiEt₃ (5 mmol), norbornene (5 mmol), Ru₃(CO)₁₂ (6 mol%), toluene (0.5 ml), reflux, 20h</p> <p>Single example, 36% mono silylation, 25% bis silylation</p>	¹⁶¹
18		Silylation	HSiEt ₃		<p>Substrate (1 mmol), HSiEt₃ (5 mmol), norbornene (5 mmol), Ru₃(CO)₁₂ (6 mol%), toluene (0.5 ml), reflux, 20h</p> <p>Single example, 56% mono silylation, 37% bis silylation</p>	¹⁶¹
19		Arylation	Ar-Br		<p>Substrate (0.5 mmol), PhBr (0.6 mmol), [RuCl₂(η⁶-C₆H₆)]₂ (0.0125 mmol), PPh₃ (0.05mmol), K₂CO₃ (1.0 - 2.0 mmol), NMP (1 mL), 120 °C, N₂, 20 h.</p> <p>1 example, 70%</p>	¹⁵⁷
20		Arylation	Ar-I		<p>Pyrazole (0.1 mmol), aryl iodide (0.3 mmol), Pd(OTf)₂(MeCN)₄ (10 mol%), Ag₂O (0.2 mmol), AcOH (1 mL), 120 °C, 24 h</p> <p>R¹ = Me, Halogen, OMe, PO(OEt)₂, COOR, CH₂OAc; R² = Alkyl</p> <p>27 examples, 28-83% yield</p> <p>2 directing groups are used for the sequential synthesis of complex pyrazole-derivatives</p>	¹⁴⁷

21		Bromination	NBS		Substrate (1 equiv), NBS (2 equiv), [RuCl ₂ (p-cymene)] ₂ (5 mol%), DMA, 80 °C, 24 h. X = Cl (20%), Br (36%).	139
22		Carbenoid insertion	$\text{F}_3\text{C}-\text{C}(\text{N}_2)=\text{CO}_2\text{Me}$ CF ₃ -carbenoid		Substrate (0.2 mmol), reagent (0.24 mmol), [Cp*RhCl ₂] ₂ (2 mol-%), AgOTf (10 mol-%), DCE (2 mL), 80 °C, 4h. R ¹ = 4-CH ₃ , 4-MeO, 4-F, H, 5 examples, 93-97%	143
23		Hydrovinylation	$\text{R}^3-\text{C}\equiv\text{C}-\text{R}^2$		Substrate (0.2 mmol), alkynes (0.2 mmol), [Rh(μ-Cl)(IPr)(η ² -coe)] ₂ (0.01 mmol) in C ₆ D ₆ (0.5 mL), 70 °C, 2h. The catalytic system is very efficient for the regioselective Markonikov-type head-to-tail dimerization of terminal alkynes to enynes. R ¹ = H, CH ₃ ; R ² = H, alkyl, aryl; R ³ = alkyl, aryl; 17 examples, 24-98%	155
24		Indole synthesis	$\text{R}^2-\text{C}\equiv\text{C}-\text{R}^3$		[RhCp*Cl ₂] ₂ (2.5 mol%), NaOAc (1 mmol), pyrazolones (0.5 mmol), and alkynes (0.5 mmol) in PhBr (2.5 mL) for 2–3 h under 130 °C. 1-(3-fluorophenyl)-3-methyl-1H-pyrazol-5(4H)-one: mixture of regioisomers was observed. Alkyl-alkyl and aryl-alkyl disubstituted alkynes underwent a cyclization process and generated pyrazolo[1,2-a]cinnolines and tautomers thereof. 23 examples, 30-81% isolated yield R ¹ = H, CH ₃ , Cl, OMe, Br, F; R ² & R ³ = Ph, aryl, alkyl	156

25		Indole synthesis			<p>Substrate (1 equiv), alkyne (1.5 equiv), $[\text{RuCl}_2(p\text{-cymene})]_2$ (2.5 mol%), NaOAc (2 equiv), PhCl, 110 °C.</p> <p>$\text{R}^1, \text{R}^2 = \text{H, Me}$; $\text{R}^3 = \text{H, Me, F, Cl, Br, CN, OCF}_3, \text{OMe, CF}_3, \text{NO}_2$; $\text{R}^4 = \text{Ph, H}$; $\text{R}^5 = \text{aryl}$</p> <p>For mono substituted alkynes H always ends up in R^4 position.</p> <p>29 examples, 53-94%.</p>	78
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Triazole derivatives in C-H activation chemistry

Even though triazole was used as DG in a silylation reaction already in 2003 (Table 5, Entry 4),¹⁶¹ it took a while until it was revisited and only in the last three years examples were reported in higher frequency, showing the potential also of this nitrogen heterocycle. Also triazole is potentially a substrate for C-H activation. For example, direct arylation of 4-phenyl-1,2,3-triazole has been reported under Pd catalysis in position 5 of the triazole ring¹⁶²⁻¹⁶⁴ which is of course somewhat detrimental for its use as DG, since DG should usually not undergo any side reactions.

Palladium catalyzed acylation using aldehydes as acyl sources have been reported by Kuang and coworkers (Table 5, Entry 1).¹⁶⁵ Triazoles directs the insertion of Pd into the *ortho* C-H bond of the N2-phenyl substituent. The aldehyde is transformed to an acyl radical by reaction with *t*-butylhydroperoxide, which then gets attached to Pd and after reductive elimination delivers the final products. Both aliphatic and aromatic aldehydes were applied and the transformation showed good functional group tolerance. Using carboxylic acids instead of aldehydes the same group reported also an acyloxylation protocol.

Triazole directed acyloxylation under Pd-catalysis using simple carboxylic acids as coupling partners was reported by the group of Kuang (Table 5, Entry 2).¹⁶⁶ Both, aliphatic and aromatic carboxylic acids were applied and also cinnamic acid derivatives gave high good results.

One of the earliest examples using triazole as DG was reported by Kakiuchi and coworkers (Table 5, Entry 4).¹⁶¹ The investigated the silylation of arenes carrying different DGs, in one case also 1-methyl-1,2,3-triazole. This Ru₃(CO)₁₂ catalyzed transformation used an excess of 5 equivalents HSiEt₃ giving a mixture of mono (14%) and bis-silylation products (46%).

The group of Ackermann reported two Ru catalyzed protocols for the direct arylation of arenes directed by 1,2,3-triazole (Table 5, Entry 6).¹⁶⁷ In the first protocol published, the aryl sources which can be applied include aryl bromides, tosylates, and also the cheap and readily available aryl chlorides. However, with triazole directing groups only examples using aryl bromides were disclosed and chlorides and tosylates were only used in combination with oxazoline, pyridine, and pyrazole directing groups. This limitation was soon erased when a slightly modified protocol allowed also the application of aryl chlorides in combination with triazole DGs (Table 5, Entry 7).¹⁶⁸

Specifically noteworthy is also the iron catalyzed arylation protocol, again developed in the Ackermann lab (Table 5, Entry 8).¹⁶⁹ The attractiveness of iron as catalyst in synthesis does not require any explanation. The catalytic system consisted of simple FeCl₃ and dppe as ligand. As aryl source a aryl Grignard reagents were required, which of course leads to certain limitations regarding functional group tolerance. Regarding the substrate scope, C(sp²)-H bonds of arenes and alkenes as well as C(sp³)-H bonds could be activated. In later work also methylation with MeMgBr was reported using almost the same catalytic system.¹⁷⁰ In this contribution a large diversity of substrates was reacted (arenes, heteroarenes, olefins and even aliphatic ones) and generally high yields were obtained. The need to use Grignard reagents is of course a drawback regarding functional group tolerance. Switching to Ru catalysis, this could be overcome and simple aryl bromides can be applied (Table 5, Entry 10).¹⁷¹

Using aryl iodides as aryl source also allowed the development of an C(sp³)-H arylation protocol under Pd-catalysis using a removable triazol based DG (Table 5, Entry 13).¹⁷² The cleavage conditions for the so called TAH group involved heating in presence of BF₃Et₂O in methanol to 100 °C for 10h. Via this protocol, the DG was removed in 86% yield and 0.86g of product was isolated, showing that this can be carried out in gram scale. It has to be mentioned that also the arylation was demonstrated to be scalable and that a stereocenter present in the substrate remained unaffected.

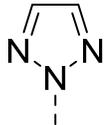
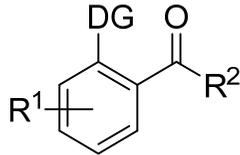
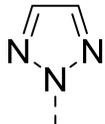
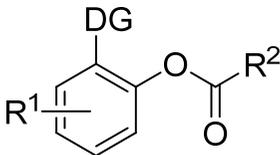
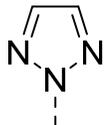
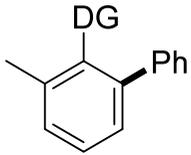
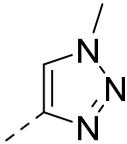
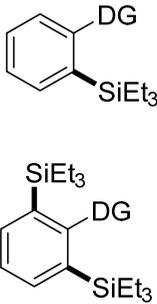
Alkenylations with acrylates are an often applied transformation in C-H activation chemistry. A triazole directed variant has been reported in the group of Shi (Table 5, Entry 12).¹⁷³ It is to mention that the DG is relatively remote from the position to be activated. Most importantly, removal of the DG was also demonstrated. Alternative reagents for alkenylations are alkynes, and also here examples with large substrate scope have been reported using triazole as DG.¹⁷⁴

The group of Shi described two relatively elaborate triazole containing directing groups, which promote actually two different transformations on the same substrate, once a substitution, more specific an acetoxylation reaction (Table, Entry), and ones an intramolecular cyclization (Table 5, Entry 14).¹⁷⁵ For the acetoxylation, *N*2-pyridine-1,2,3-triazole-4-carboxylic acid is the precursor of the DG, abbreviated TA-Py. The acid functionality is used to attach the substrate to be functionalized by forming an amide bond. Using a system of Pd(OAc)₂, PhI(OAc)₂, and AgOAc both, C(sp²)-H and C(sp³)-H bonds can be functionalized, the latter requiring somewhat harsher reaction conditions (80 °C sp² vs 140 °C sp³). Noteworthy, halide substituents in the starting material were well tolerated, which is remarkable in presence of Pd(OAc)₂.

In the same contribution *N*1-aryl-1,2,3-triazole-4-carboxylic acid was introduced as precursor for another DG, abbreviated TAA (Table 5, Entry 15).¹⁷⁵ In this case indoline and azetidine formation was obtained via intramolecular cyclization reactions. Reaction conditions required again of Pd(OAc)₂ and PhI(OAc)₂ but no AgOAc and halide substituents were once more unaffected and well tolerated. As could be expected, the more strained ring system azetidine required higher temperature for the cyclization to take place (120 °C vs. 80 °C). It is important to note that cleavage of the TAA group has been demonstrated in one example giving indoline in 95% and also the DG precursor was isolated in 82% yield.

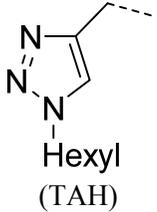
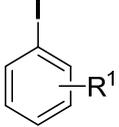
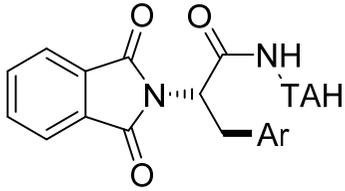
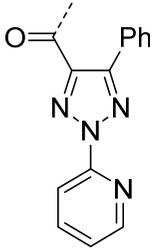
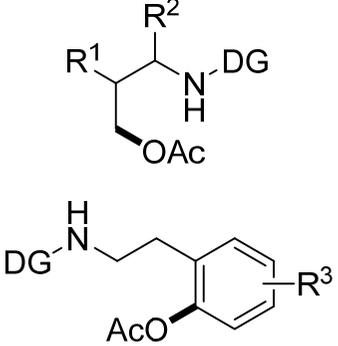
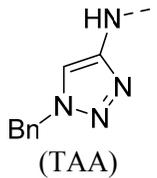
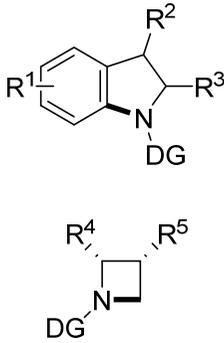
So far 1,2,3-triazoles were the DG of choice. Punniamurthy and coworkers applied also a 1,2,4-triazole derivative as DG in their copper catalyzed nitration of arenes using simple Fe(NO₃)₃·9H₂O as NO₂ source (Table 5, Entry 16).¹⁷⁶ Noteworthy, only 35 mol% Fe(NO₃)₃·9H₂O were used to get yields >80% in the nitration process indicating that all three NO₃ groups are transferable.

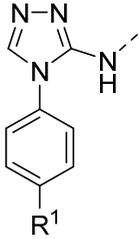
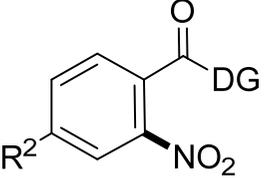
Table 5: Triazole derivatives in C-H activation chemistry

Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
1		Acylation	R ² CHO		Substrate (0.4 mmol), aldehyde (0.44 mmol), Pd(OAc) ₂ (10 mol%), TBHP (0.4 mmol, 70 wt % in water), DCE (2 mL) at 80 °C for 15 h in pressure tubes. R ¹ = H, Me, Cl, COOMe, OMe; R ² = aryl, alkyl; 26 examples, 25-85%	¹⁶⁵
2		Acyloxylation	R ² COOH		Substrate (0.4 mmol), carboxylic acid (0.48 mmol), Pd(OAc) ₂ , (10 mol%), K ₂ S ₂ O ₈ (0.8 mmol, 2 equiv), DCE (2 mL) for 20 h in pressure tubes. R ¹ = H, Cl, COOMe, OMe; R ² = alkyl, aryl, alkenyl; 25 examples, 52-86% The C-H cleavage being the rate-limiting step	¹⁶⁶
3		Arylation	Ar-Br		Substrate (0.5 mmol), PhBr (0.6 mmol), [RuCl ₂ (η ⁶ -C ₆ H ₆)] ₂ (0.0125 mmol), PPh ₃ (0.05mmol), K ₂ CO ₃ (1.0 - 2.0 mmol), NMP (1 mL), 120 °C, N ₂ , 20 h. 1 example, 82%.	¹⁵⁷
4		Silylation	HSiEt ₃		Substrate (1 mmol), HSiEt ₃ (5 mmol), norbornene (5 mmol), Ru ₃ (CO) ₁₂ (6 mol%), toluene (0.5 ml), reflux, 20h Single example, 14% mono silylation, 46% bis silylation	¹⁶¹

5		Alkenylation	$R^3 \equiv R^4$		[RuCl ₂ (<i>p</i> -cymene) ₂] (5 mol %), Cu(OAc) ₂ ·H ₂ O (20 mol%), AgSbF ₆ (20 mol%), toluene, 100 °C, 2.5 h R ¹ = Bn, <i>p</i> -subst-Bn, undecal, cyclohexyl, CH ₃ CHPh, (CH ₃) ₂ CPh; R ² = H, Me, Cl, F, CF ₃ , NO ₂ , OMe; in most cases R ³ = R ⁴ = Ph resp. 4 subst. phenyl (Me, OMe, Cl, CF ₃); 2 examples for R ³ = alkyl (Me or <i>n</i> hex) and R ⁴ = Ph; 25 examples, 52-91%	174
6		Arylation			[RuCl ₂ (<i>p</i> -cymene) ₂] (2.5 mol %), MesCOOH (30 mol %), toluene, K ₂ CO ₃ , 120 °C, 16-20h R ¹ = Bu, CH ₂ TMS, hexyl; R ² = 2-Me, 2-MeO; R ³ = Cl, Me, OMe, CPh, COMe, COOEt; 8 examples, 63-97%;	167
7		Arylation			[RuCl ₂ (<i>p</i> -cymene) ₂] (2.5 mol %), PCy ₃ (10 mol %), NMP, K ₂ CO ₃ , 120-135 °C, 20h R ¹ = Bu, CH ₂ TMS, hexyl; R ² = 2-Me, 3-Me, 2-MeO; R ³ = OMe, CPh, COOR, OTs; 12 examples, 50-94%; In 4-chlorobromobenzene the bromine reacted exclusively.	168
8		Arylation			Substrate (0.3 mmol), ArMgBr (2.1 mmol), FeCl ₃ (10 mol-%), dppe (10 mol-%), ZnBr ₂ ·TMEDA (3 equiv), DCIB (2 equiv), THF (1 mL), 55 °C. R ¹ = H, Me, F, MeO; R ² = H, Me, MeO, F, Et, Ph; 21 examples, 51-93% DG removal in aq. HCl.	169
9		Arylation			Substrate (0.2 mmol), ArMgBr (1.4 mmol), FeCl ₃ (20 mol-%), dppe (20 mol-%), ZnBr ₂ ·TMEDA (3 equiv), DCIB (2 equiv), toluene (1 mL), 80 °C. R ¹ = H, Me, F, MeO; R ² = Me, cyclohexyl;	169

	(TAM)				9 examples, 52-87%	
10	 (TAM)	Arylation	ArBr		Substrate (1 equiv), ArBr (1.2 equiv), Na ₂ CO ₃ (1.5 equiv), [RuCl ₂ (PPh ₃) ₃](5 mol%), <i>o</i> -xylene (0.25 M), 22 h, 120–140 °C. Reaction might involve SET-type process. R ¹ includes H, Me, OMe, CF ₃ , Ph, Cl, F 25 examples, 11-99%	¹⁷¹
11	 (TAM)	Methylation	MeMgBr		Substrate (1 equiv), MeMgBr (7 equiv), FeCl ₃ (20 mol-%), dppe (20 mol-%), ZnCl ₂ .TMEDA (3 equiv), DCIB (2 equiv), THF, 25-55 °C. Functional group tolerance limited as expected for a large excess of Grignard reagent (R ² = Me, OMe); Substrates structurally quite diverse; also heterocyclic substrates applied; also olefins and alkanes instead of arene substrates; 26 examples, 49-99%.	¹⁷⁰
12	 TA(Ph)	Alkenylation			Substrate (0.2 mmol), alkene (0.8 mmol), HOAc (5.0 mmol), Pd(OAc) ₂ (7.5-15 mol%), Cu(OTf) ₂ (10 mol%), 105-115 °C, O ₂ balloon or 1 atm of O ₂ in sealed tube, 1,4-dioxane (1.0mL). A primary KIE was observed (KH/KD=2.1) suggesting rather a C–H activation than a Lewis acid catalyzed Friedel–Crafts-type mechanism Removal of the Dg using Boc ₂ O then LiOH/H ₂ O ₂ furnished the Boc protected amines. R ¹ = H, Me, OMe, F, Br; R ² = COOBu, CN, Me, NMe ₂ , PO(OEt) ₂ , Ph, SO ₂ Ph, aryl; 25 examples, 78-95%; in some	¹⁷³

					cases mixtures of mono and bis alkenylated products were obtained	
13	 <p>Hexyl (TAH)</p>	Arylation			<p>Substrate (0.40 mmol), Pd(OAc)₂ (10.0 mol%), ArI (0.60 mmol, 1.5 equiv), AgOAc (0.60 mmol, 1.5 equiv), HFIP (2 mL), 100 °C, 5 h</p> <p>R¹ = MeO, F, Cl, Br, NO₂, Me, CF₃, COOMe, Ph, COEt; 16 examples, 68-90%</p> <p>DG removal: use BF₃.Et₂O, MeOH, 100 °C, 10h</p>	172
14	 <p>TA-Py</p>	Acetoxylation	PhI(OAc) ₂		<p>C(sp³)-H activation: Pd(OAc)₂ (10 mol%), PhI(OAc)₂ (3.0 equiv), AgOAc (1.5 equiv) in DCE, Ar atmosphere, 140 °C, 24h.</p> <p>R¹ = COOMe, CH₂OAc; R² = Me, Et; 4 examples, 58-76%</p> <p>C(sp²)-H activation: Pd(OAc)₂ (10 mol%), PhI(OAc)₂ (2.5 – 3.0 equiv), AgOAc (0.5 equiv) in DCE, Ar atmosphere, 80 °C, 24h.</p> <p>R³ = H, Me, Br, F, OMe, I; 15 examples 60-85%</p> <p>For both activation types mixtures of mono and bis substitution are sometimes formed.</p>	175
15	 <p>(TAA)</p>	Cyclization	-		<p>Indoline formation: Pd(OAc)₂ (5 mol%), PhI(OAc)₂ (2.0 equiv), in DCE, Ar atmosphere, 80 °C, 24h.</p> <p>R¹ = F, Br, I, Me, MeO; R² = H, Me; R³ = H, COOMe; 12 examples, 53-85%</p> <p>Azetidine formation: Pd(OAc)₂ (5 mol%), PhI(OAc)₂ (2.5 equiv), in DCE, Ar atmosphere, 120 °C, 24h.</p> <p>R⁴ = COOMe, CH₂OAc, Me; R⁵ = Me, Et;</p> <p>4 examples, 56-88%</p>	175

16		Nitration	$\text{Fe}(\text{NO}_3)_3 \cdot 9\text{H}_2\text{O}$		Substrate (1 mmol), $\text{CuCl}_2 \cdot 2\text{H}_2\text{O}$ (20 mol%), $\text{Fe}(\text{NO}_3)_3 \cdot 9\text{H}_2\text{O}$ (35 mol%), DCE (3 mL), rt. $\text{R}^1 = \text{R}^2 = \text{H, F, Me}$; 3 examples, 82-87%	176
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Tetrazole derivatives in C-H activation chemistry

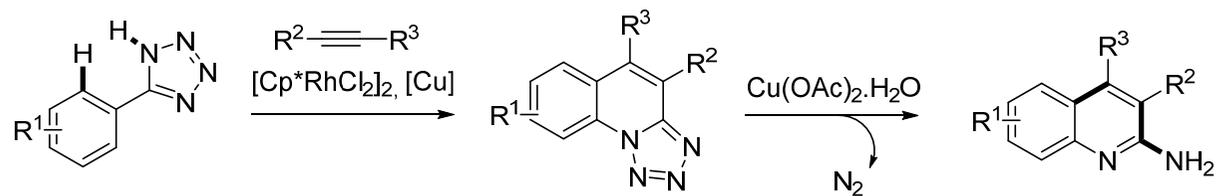
Not surprisingly also tetrazoles are potential DGs. In case they are attached to the substrate via the remaining carbon of the ring, a competitive C-H activation of the DG is not an issue. Still, only few examples have been reported so far. Tetrazoles are of increasing importance in medicinal chemistry due to the fact that they are considered as bioisosters of carboxylic acids.¹⁷⁷⁻¹⁸¹ Hence, it can be expected that the amount of examples using tetrazoles as DGs will be increasing in the near future. One of the earliest examples using tetrazoles as DGs was reported by Kakiuchi and coworkers.¹⁶¹ They investigated the silylation of arenes carrying different DGs, in two cases differently methylated (N1 and N2) tetrazoles. This $\text{Ru}_3(\text{CO})_{12}$ catalyzed transformation used an excess of 5 equivalents HSiEt_3 giving a mixture of mono (22%) and bis-silylation products (71%) in case of N2 methylated tetrazole but only the mono-silylated product in case of N1 methylated tetrazole. Eventually, the DG cannot rotate around the C-C bond to present the sp^2 nitrogen to the second ortho position due to steric hindrance between the N1 methyl group and the bulky SiEt_3 group. This is actually a general finding since several other examples with this directing group show a selective mono substitution (Table 6, Entries 4-6) for examples where other DGs give also bis-substitution.

Oxidative alkenylations with acrylates¹⁸² (and in one case styrene) and hydroarylation alkenylations with alkynes¹⁸³ have been reported using the same Rh species, namely $[\text{RhCp}^*(\text{MeCN})_3]\text{SbF}_6$ (Table 6, Entries 1 & 2). Both transformations show a broad functional group tolerance, including reactive halides such as Br, important for further elaboration of the products.

The group of Seki has reported tetrazole directed ortho arylation due to their interest of efficient synthesis of angiotensin II receptor blockers (Table 6, Entry 11).¹⁸⁴⁻¹⁸⁷ They explored various N1 substituted tetrazoles under Ru catalysis using bromobenzenes as the aryl source. However, the substrate scope regarding the aryl source was not fully explored and seems to be quite limited.

A much more comprehensive study regarding the aryl bromide substrate scope was reported by Ackermann and coworkers (Table 6, Entry 9)¹⁸⁸. A bulky carboxylic acid as additive improved the yield significantly. Importantly, also two heterocyclic aryl bromides were successfully coupled. 2-Bromothiophene gave a good yield of product of 63%, whereas 3-bromopyridine gave only 30% yield. due to the N1-benzyl group in the DG, only mono-arylation products were observed.

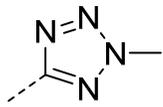
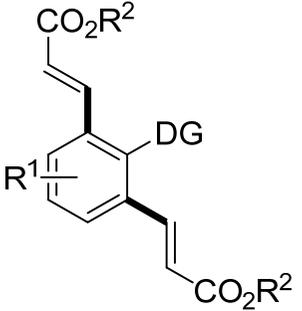
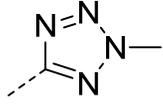
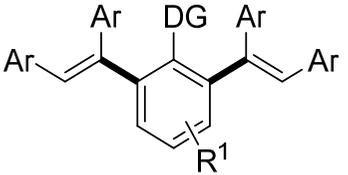
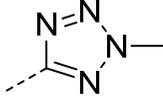
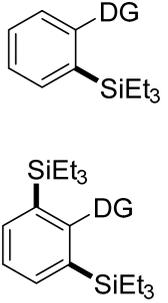
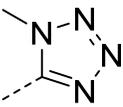
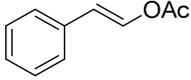
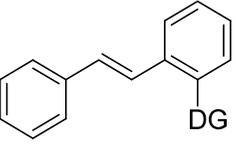
An interesting quinolone synthesis has been reported by Hua and coworkers (Table 6, Entry 13)¹⁸⁹. Initially, N1-aryl tetrazoles undergo a cyclization with internal alkynes under Rh-catalysis. The so obtained intermediate fragments and eliminates N_2 mediated by $\text{Cu}(\text{OAc})_2 \cdot \text{H}_2\text{O}$ (Scheme 4). Interestingly, water free $\text{Cu}(\text{OAc})_2$ gives only low yields of the quinolones whereas the mono hydrate gives almost quantitative conversion. In most cases symmetrical diarylalkynes were used. In cases where mixed alkyl-aryl alkynes were used, the alkyl residue ended up in R^3 position with high regioselectivity.



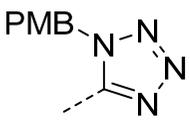
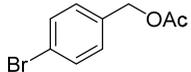
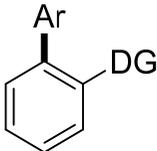
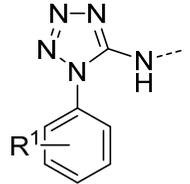
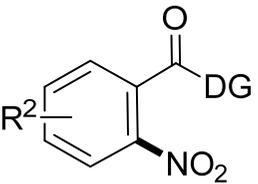
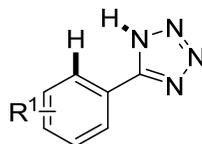
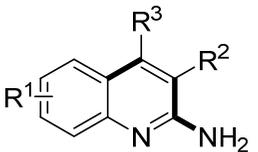
Scheme 4: Tetrazole directed annulation/N₂ extrusion towards 2-aminoquinolines.

A convenient nitration protocol was reported by Punniyamurthy and coworkers (Table 6, Entry 12).¹⁷⁶ As nitrating agent Fe(NO₃)₃·9H₂O was used and cheap CuCl₂ could be used as catalyst. Such methods are extremely interesting since the ortho directing group, 1-aryl tetrazoles in this case, can override the directing effects substituents already present in the starting material might have. Overall, 21 examples with high yields have been reported. Since the DG is attached via an NH linker to the substrate, it could also be cleaved afterwards, giving 2-nitro substituted anilines. In one case the transformation was also carried out in gram scale with no decreased yield.

Table 6: Tetrazole derivatives as directing groups in C-H activation reactions

Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
1		Alkenylation			Substrate (0.1 mmol), acrylates (0.2 mmol), [RhCp*(MeCN) ₃][SbF ₆] ₂ (5 mol-%), Cu(OAc) ₂ (2 equiv), dioxane (1.5 mL), 110 °C, air, 12 h. Works with styrene but not acrylonitrile. C-H bond cleavage was the rate-determining step R ¹ = H, Me, OMe, Br, F, CF ₃ , CN, NO ₂ , Cl; R ² = Me, Et, <i>t</i> -Bu; 16 examples, 22-95%	¹⁸²
2		Alkenylation			Substrate (0.2 mmol), reagent (0.6 mmol), [RhCp*(MeCN) ₃][SbF ₆] ₂ (2 mol%), PhCOOH (0.05 mmol), HOAc (2 mL), 80 °C Ar = Ph, 4-MeC ₆ H ₄ , 4-MeO C ₆ H ₄ , 4-Br C ₆ H ₄ , 4-Cl C ₆ H ₄ , 4-FC ₆ H ₄ , R ¹ = H, Me, MeO, Br, F, CF ₃ , COOH, Cl; 16 examples, 57-94%.	¹⁸³
3		Silylation	HSiEt ₃		Substrate (1 mmol), HSiEt ₃ (5 mmol), norbornene (5 mmol), Ru ₃ (CO) ₁₂ (6 mol%), toluene (0.5 ml), reflux, 20h Single example, 22% mono silylation, 71% bis silylation	¹⁶¹
4		Alkenylation			Substrate (1 mmol), alkene source (3 mmol), 3 (0.05mmol), toluene (1.5 mL), reflux, isolated yield. Mono selective, single example, 52%	¹⁹⁰

5		Arylation	PhBr		Substrate (0.5 mmol), PhBr (0.6 mmol), [RuCl ₂ (η ⁶ -C ₆ H ₆)] ₂ (0.0125 mmol), PPh ₃ (0.05mmol), K ₂ CO ₃ (1.0 - 2.0 mmol), NMP (1 mL), 120 °C, N ₂ , 20 h. Mono selective, single example, 43% yield	157
6		Iodination	NIS		Pd(OAc) ₂ (5 mol%), NIS (1.05–2.1 equiv), 100–120 °C, 12 h, MeCN or AcOH. Mono selective, single example, 41%	160
7		Silylation	HSiEt ₃		Substrate (1 mmol), HSiEt ₃ (5 mmol), norbornene (5 mmol), Ru ₃ (CO) ₁₂ (6 mol%), toluene (0.5 ml), reflux, 20h Single example, 70% mono silylation	161
8		Arylation	ArI		Substrate (0.2 mmol, 1.0 equiv), reagent (10.0 equiv), Pd(OAc) ₂ (5 mol%), AgOAc(4.0 equiv), TFA (0.2 mL), 150°C, 24h R = H, Me, MeO, F, Cl, Br; 6 examples, 43-85%	191
9		Arylation	ArBr		Substrate (1 equiv), ArBr (1.1 equiv), [RuCl ₂ (<i>p</i> -cymene)] ₂ (5 mol%), MesCOOH (30 mol%), K ₂ CO ₃ (2 equiv), toluene, 120 °C, 18 h; Selective mono arylation; also heterocyclic bromides could be applied; ArBr carrying ketones, esters, methyl, methoxy, and fluorine were reported; 21 examples, 30-70%.	188
10		Arylation	PhI		Substrate (0.2 mmol, 1.0 equiv), reagent (10.0 equiv), Pd(OAc) ₂ (5 mol%), AgOAc(4.0 equiv), TFA (0.2 mL), 150°C, 24h R = H, Me, OMe, F, Cl, Br; 6 examples, 65-96%. Substrates carrying already a substituent in <i>ortho</i> or <i>meta</i> position gave high yields of mono arylation: 18 examples,	191

					59-97%. Also 1-Bn-tetrazole used as DG, then selective mono arylation, same 6 examples 43-88% yield.	
11		Arylation			Substrate (1 equiv), ArBr (1.1 equiv), K ₂ CO ₃ (2 equiv), RuCl ₃ ·xH ₂ O (10 mol%), PPh ₃ (18 mol%), 140 °C, 12 h 81% of single example	187
12		Nitration	Fe(NO ₃) ₃ ·9H ₂ O		Substrate (1 mmol), CuCl ₂ ·2H ₂ O (20 mol%), Fe(NO ₃) ₃ ·9H ₂ O (35 mol%), DCE (3 mL), rt. Reaction was scaled up to gram scale DG removal: 7 equiv NaOH in dioxane, 110 °C, 12-22 h. Substrate-binding step is the product-determining step. TEMPO does not inhibit the reaction. R ¹ = H, Me, Cl, F, OMe, <i>i</i> Pr, Et; R ² = H, F, <i>i</i> Pr, naphthyl, NO ₂ , Et, Me, CN, NHAc; 22 examples, 77-95%	176
13		Quinoline synthesis	R ² ≡R ³		Substrate (2.5 equiv), alkyne (1 equiv), [Cp*RhCl ₂] ₂ (2.5 mol%), Cu(OAc) ₂ ·H ₂ O (2 equiv), KOAc (2 equiv), DMAc, 130 °C, N ₂ , 6 h R ¹ = H, Me, MeO, Et, <i>i</i> Pr, <i>t</i> Bu, F, Cl, COOMe, COCF ₃ ; R ² = R ³ in most cases and aryl, four alkyl-aryl alkynes were included and high regioselectivity was observed whereas R ³ = alkyl, R ² = aryl. 24 examples overall, 46-79%.	189

Oxazole based directing groups

Oxazole itself is rarely applied as DG since its C2 and C5 position can be readily C-H activated themselves.¹⁹² The much more frequently applied variant is oxazoline, typically attached via C2 to the substrate to be activated. Even though not shown in many contributions, oxazoline is a cleavable DG since it can be hydrolyzed to a carboxylic acid,¹⁹³⁻¹⁹⁵ which in turn can be further transformed into other functional groups or eventually removed by decarboxylation. From this point of view, oxazoline is a very attractive DG. The basic sp² hybridized nitrogen allows similar transformations as with other N-heterocycles such as pyridine, pyrimidine, pyrazole, and so on. Not surprising, many contributions which are dedicated to either of these other N-heterocyclic DGs, also show one or the other example in which it is demonstrated that the developed methodology also tolerates oxazoline as a DG. The discussion of examples in this section is however focused on examples which have oxazole derivatives as the main focal point in their research.

Oxazoline was very early established as suitable DG in C-H activation chemistry. Murai and coworkers established Ru₃(CO)₁₂ catalyzed carbonylation using CO and an olefine (in most cases ethylene) as coupling partner (Table 7, Entry 17).¹⁹⁶ This is one of the pioneering early examples of C-H activation chemistry. If two ortho positions on the arene substrates were available, mixtures of mono and bis substituted products were obtained. Blocking one ortho position naturally led to selective reactions. Even in presence of one *meta* substituent, the two remaining ortho positions were significantly different in reactivity and carbonylation occurred mainly at the sterically less compromised side, eventually accompanied by bis-carbonylated products. When higher olefins were used, mixtures of linear and branched ketone products were obtained. This study focused on oxazoline, however also several other DGs were reported, amongst them oxazole itself (Table 7, Entry 1), which proved to be significantly less efficient.

Kakiuchi reported Ru₃(CO)₁₂ catalyzed silylation with a series of DGs (Table 7, Entry 18).¹⁶¹ As starting point in their development served 4,4-dimethyloxazoline and high yields of the mono-silylation products were obtained. Twofold silylation, which was often an issue with other DGs was never an issue in the oxazoline directed case.

An interesting alkylation using tetraalkyl tin reagents was reported by the group of Yu (Table 7, Entry 12).¹⁹⁷ It turned out that batch wise addition of the organotin reagent over prolonged reaction times (up to 60h) was necessary in order to get good yields. The reactions could be accelerated significantly when carried out in the microwave.

Nishimura reported a branch-selective alkylation of arenes with vinyl ethers (or hydroarylation of vinyl ethers) using an iridium catalyst (Table 7, Entry 13).¹⁹⁸ Even though only one example with an oxazoline DG has been reported (majority of examples on 2-phenylpyridines), it is worth mentioning since usually only linear alkylation products are obtained.

Alkylation and arylation with alkyl or aryl iodides has been reported by the group of Liu (Table 7, Entries 33 & 34).¹⁹⁹ In this case, an isoxazole containing directing group was used. Remarkable is the functional group tolerance, which was especially demonstrated for the arylation case. Here, it was shown that halides were well tolerated and also a boronic ester, nitro and an azide group gave high yields.

Shi and coworkers reported the remote activation and arylation with aryl iodides of γ -methylene C(sp³)-H bonds (Table 7, Entry 15) and δ -C(sp²)-H bonds (Table 7, Entry 16) using an amide linked oxazoline directing group.²⁰⁰ A remarkably large functional group tolerance was reported. Additionally, it is a rare example in which cleavage of the oxazoline DG was really tested and successfully carried out.

Bidentate amino oxazoline directing groups, chiral and achiral ones, have been used for the direct arylation of secondary C-H bonds by the group of Shi (Table 7, Entry 24).²⁰¹ Reaction optimization started with Pd(OAc)₂ as catalyst and carboxylic acids as additives, a typical combination to start a screening in the field. Interestingly, dibenzyl phosphate ((BnO)₂PO₂H) proved to be more affective, in the end in combination with Pd(OPiv)₂ as palladium source. Iodo arenes had to be used as aryl source and it was shown that many functional groups were well tolerated. Only sterically demanding 2-iodotoluene gave no conversion. Also C(sp²)-H activation was tried using this protocol but no conversion was observed. Additionally, a chiral variant of the DG was applied and three examples with d.r. of 88:12 – 90:10 were reported (Table 7, Entry 25). Alternative aryl sources have been applied as well, e.g. aryl tosylates (Table 7, Entry 6)²⁰² and aryl bromides (Table 7, Entry 8).²⁰³

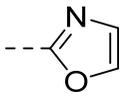
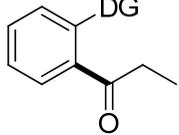
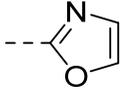
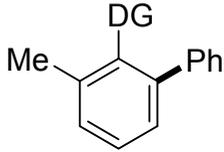
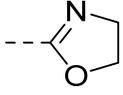
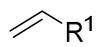
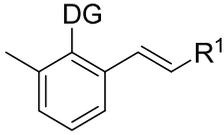
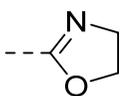
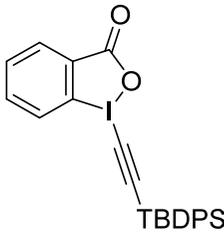
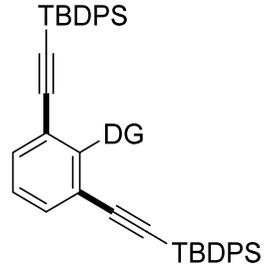
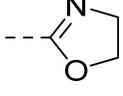
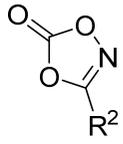
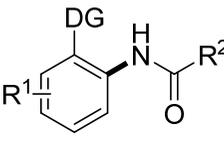
Asymmetric iodination was reported by the group of Yu under mild conditions (Table 7, Entry 23).²⁰⁴ Four examples with a chiral DG were reported giving d.r. between 91:9 and as high as 99:1. Naturally, the reaction was also carried out in a racemic fashion as well, with typically high yields of up to 97%. In subsequent years the method was further explored in a series of papers^{205, 206} and also detailed mechanistic investigations were reported.²⁰⁷ The group of Sanford also reported a single example for an isoxazoline directed iodination, this time using NIS as iodination reagent (Table 7, Entry 35).¹⁶⁰

A copper catalyzed method for the coupling of amides with malonates was reported by Dai and Yu (Table 7, Entry 26).²⁰⁸ The initial C-H activation and C-C coupling reaction with malonates was followed by an intramolecular oxidative C-N bond formation, ultimately leading to isoindolin-1-ones. The functional group tolerance was good, yields however were often only around 50%.

Besides oxazoline, also benzoxazole can be used as DG since in that case positions 4 and 5 are blocked due to annulation and C2 is typically used to attach the substrate. A comprehensive study of the ortho acylation of 2-arylbenzoxazoles has been reported by the group of Yang and Wu (Table 7, Entry 29-31).²⁰⁹ Aldehydes were applied as readily available acyl source, which are transformed to acyl radicals by action of the organic oxidant TBHP. Only aromatic aldehydes were applied and in most cases and a large excess of 6 equivalents was required.

Amidation using 3-substituted 1,4,2-dioxazol-5-ones as amide source has been reported by Ackermann and coworkers under Co-catalysis using several different DGs, amongst them oxazoline and 5,6-dihydro-4H-1,3-oxazine (Table 7, Entries 5, 20-22, 36).¹⁵ Such a method leads to regioisomeric amides as compared to the isocyanate method established by Shibata (Table 7, Entry 19)²¹⁰.

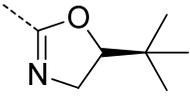
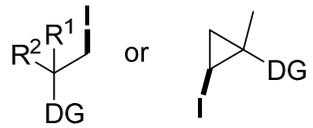
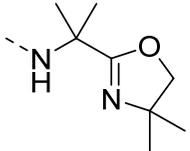
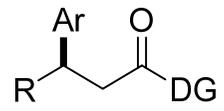
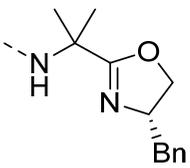
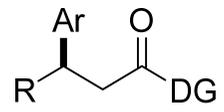
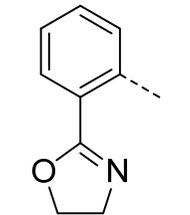
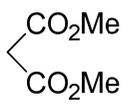
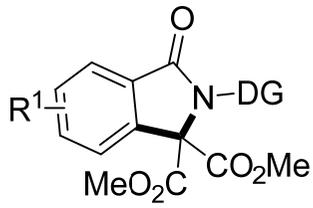
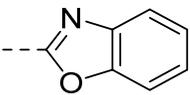
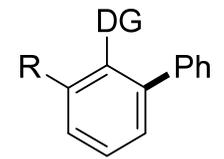
Table 7: Oxazole based and related directing groups in C-H activation chemistry

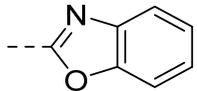
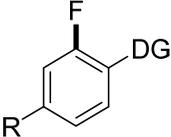
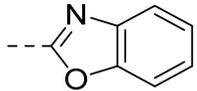
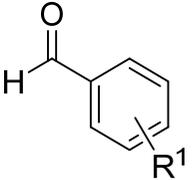
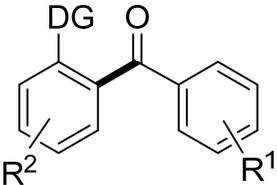
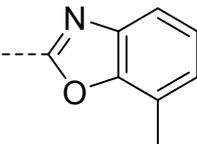
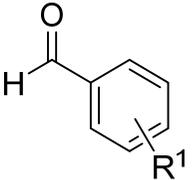
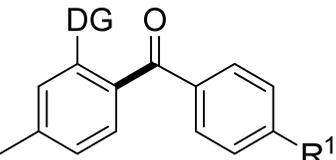
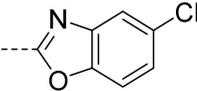
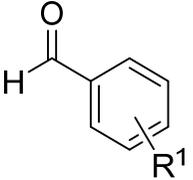
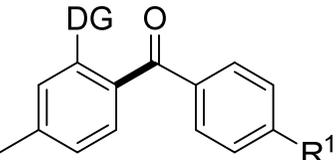
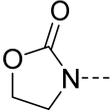
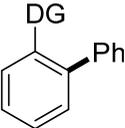
Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
1		Carbonylation	CO, CH ₂ =CH ₂		5 mol% Ru ₃ (CO) ₁₂ , ethylene, CO, 20 atm, toluene, 160 °C, 40h Single example, 36%	¹⁹⁶
2		Arylation	Ar-Br		Substrate (0.5 mmol), PhBr (0.6 mmol), [RuCl ₂ (η ⁶ -C ₆ H ₆) ₂] (0.0125 mmol), PPh ₃ (0.05mmol), K ₂ CO ₃ (1.0 - 2.0 mmol), NMP (1 mL), 120 °C, N ₂ , 20 h. Single example, 66%	¹⁵⁷
3		Alkenylation			Substrate (1 equiv), alkene (1.3 equiv), [RuCl ₂ (<i>p</i> -cymene) ₂] (5 mol%), 1,1'-binaphthyl-2,2'-diyl hydrogenphosphate (10 mol%), Cu(OAc) ₂ .H ₂ O (0.8 equiv), EtOH (2 mL), 80 °C under air. R ¹ = various esters, alkyls and aryls, amides; 10 examples, 15-80%	²¹¹
4		Alkynylation			Substrate (0.2 mmol), R-EBX (0.46 mmol), [RhCp*Cl ₂] ₂ (2 mol%), Zn(OTf) ₂ (0.02 mmol, 10 mol%), DCE (2mL), 25 °C, 16 h; 1 example, 73%	²⁸
5		Amidation			Substrate (1 equiv), dioxazolone (1.2 equiv), Cp*Co(CO)I ₂ (5 mol%), AgSbF ₆ (20 mol%), NaOAc (20 mol%), DCE, 100 °C, 20 h. R ¹ = H, Me, Et, <i>i</i> Pr, OMe, O _t Bu, Ph, CF ₃ , F, Cl, Br, CO ₂ Me, NHAc, Cl; R ² = Ph, 3-F-C ₆ H ₄ ; 18 examples, 50-75%	¹⁵

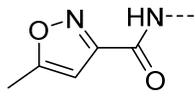
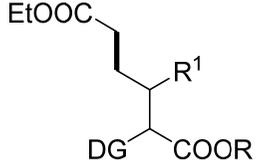
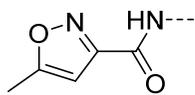
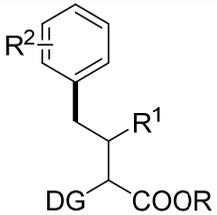
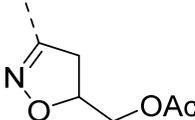
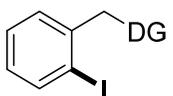
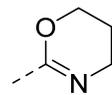
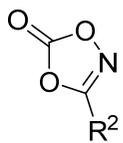
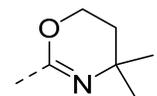
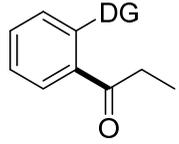
6		Arylation	Ar-OTs		Substrate 1 equiv, Ar-OTs (1.2 equiv), [RuCl ₂ (<i>p</i> -cymene)] ₂ (2.5 mol%), ligand (10 mol%), K ₂ CO ₃ , NMP, 120 °C, 23 h Ar substituents: OMe, Me, styrene, COOR, CN, CF ₃ , COPh, COMe; 12 examples, 50-96%.	202
7		Arylation	PhCl		2-Phenyloxazoline (0.5 mmol), ArCl (1.25 mmol, 2.5 equiv), [RuCl ₂ (<i>p</i> -cymene)] ₂ (2.5 mol%), KOPiv (10 mol%), K ₂ CO ₃ , (3 equiv), DEC (2 mL); 1 example, 96%.	158
8		Arylation	Ar-Br		[RuCl ₂ (<i>p</i> -cymene)] ₂ (5 mol%), KOAc (20 mol%), PPh ₃ (10 mol%), K ₂ CO ₃ (4 equiv), H ₂ O (2 mL), 110 °C, 20 h R = H, Me, F, CF ₃ , OMe, Cl; 6 examples, 12-87%	203
9		Cyanation			Substrate (1 equiv), cyanating reagent (2 equiv), [RhCp*(CH ₃ CN) ₃](SbF ₆) ₂ (5 mol%), Ag ₂ CO ₃ (20 mol %), dioxane. Single example, 76%	212
10		Alkenylation			Substrate (1 mmol), alkene source (3 mmol), Ru(cod)(cot) (0.05mmol), 2,6-lutidine (2 mmol), toluene (1.5 mL), reflux, 40 h. Single example, 69%	190
11		Alkenylation			Substrate (1 equiv), alkene (1.3 equiv), [RuCl ₂ (<i>p</i> -cymene)] ₂ (5 mol%), 1,1'-binaphthyl-2,2'-diyl hydrogenphosphate (10 mol%), Cu(OAc) ₂ ·H ₂ O (0.8 equiv), EtOH (2 mL), 80 °C under air. R ¹ = various esters, alkyls and aryls, amides; R ² = H, Me; 6 examples, 32-81%	211

12		Alkylation	R ₄ Sn	<p>or</p>	<p>Pd(OAc)₂ (10 mol%), organotin reagent (0.75 equiv in 10 batches a 0.075 equiv or as 20 batches a 0.037 equiv), Cu(OAc)₂ (1 equiv), benzoquinone (1 equiv), MeCN, 100 °C, 40-60h</p> <p>R¹ = Me, Et, Pr, Bu, Oct; 19 examples, 62-90%.</p> <p>Cyclic substrates included cyclopropyl, cyclopentyl and cyclohexyl</p> <p>Microwave irradiation reduced the reaction time to 10h</p>	197
13		Alkylation			<p>Substrate (1 equiv), olefin ether (1.5 equiv), [IrCl(cod)]₂ (5 mol% Ir), NaBAR^F₄ (10 mol %), toluene, 80 °C, 48 h.</p> <p>1 example, 94%; gives selectively the branched product!</p>	198
14		Arylation	Ar-H		<p>Pd(OAc)₂ (10 mol%), Cu(OAc)₂ (2 equiv), benzene, K₂CO₃ (2.3 equiv), 120 °C, sealed tube</p> <p>39% bis-arylation, 4% mono-arylation</p> <p>Only example catalytic in Pd</p>	213
15		Arylation	Ar-I		<p>Pd(OAc)₂ (5 mol%), Ar-I (3 equiv), Ag₂CO₃ (2 equiv), 1-AdCOOH (0.5 equiv), DCE, N₂, 110 °C, 24h</p> <p>R = Et, Pr, <i>n</i>Bu, CH₂Cy, <i>n</i>heptyl, CH₂CF₃, <i>i</i>Bu, (CH₂)₂Ph, and others; Substituents on Ar reported: Et, Ac, OMe, NHAc, F, Cl, OAc, CF₃, CO₂Me, CN, NO₂; 28 examples, 15-83%.</p> <p>Cleavage of DG: 6M HCl reflux, then NaOH, 1 example, 62%</p>	200
16		Arylation	Ar-I		<p>Pd(OAc)₂ (10 mol%), Ar-I (3 equiv), Ag₂CO₃ (2 equiv), 1-AdCOOH (0.5 equiv), DCE, N₂, 110 °C, 24h</p> <p>Substituents on Ar reported: Ac, OMe, NHAc, F, CF₃, CO₂Me, NO₂; 7 examples, 27-80%.</p>	200

17		Carbonylation	CO, CH ₂ =CH ₂		5 mol% Ru ₃ (CO) ₁₂ , ethylene, CO, 20 atm, toluene, 160 °C R ¹ = Me, CF ₃ , OMe, F, Ph, Me ₃ Si, CH ₂ SiMe ₃ , OTBDMS, Br, Cl, CN, NMe ₂ ; 17 examples, up to 98% yield.	196
18		Silylation	HSiEt ₃		Substrate (1 mmol), HSiEt ₃ (5 mmol), norbornene (5 mmol), Ru ₃ (CO) ₁₂ (6 mol%), toluene (0.5 ml), reflux, 20h. R ¹ = H, F, Me, OMe, CF ₃ ; 8 examples, 26%-quant yield. CF ₃ in 2 position gave the low yield of 26%, all other examples were significantly better.	161
19		Amidation	R-NCO		[RhCp*(OAc) ₂ (H ₂ O)] (5 mol%), HBF ₄ .Et ₂ O (10 mol%), THF, 75 °C; R = Ph, 4-MeC ₆ H ₄ , 4-ClC ₆ H ₄ , Bn, <i>n</i> Bu, cyclohexyl; 6 examples, 24-69% Single diastereomer.	210
20		Amidation			Substrate (1 equiv), dioxazolone (1.2 equiv), Cp*Co(CO)I ₂ (5 mol%), AgSbF ₆ (20 mol%), NaOAc (20 mol%), DCE, 100 °C, 20 h. Single example, 85%	15
21		Amidation			Substrate (1 equiv), dioxazolone (1.2 equiv), Cp*Co(CO)I ₂ (5 mol%), AgSbF ₆ (20 mol%), NaOAc (20 mol%), DCE, 100 °C, 20 h. Single example, 74%	15
22		Amidation			Substrate (1 equiv), dioxazolone (1.2 equiv), Cp*Co(CO)I ₂ (5 mol%), AgSbF ₆ (20 mol%), NaOAc (20 mol%), DCE, 100 °C, 20 h. Single example, 86%	15

23		Iodination	I_2		10 mol% Pd(OAc) ₂ , PhI(OAc) ₂ (1 equiv), I ₂ (1 equiv), DCM, 24 – 50 °C 4 examples, 62-98%, 91:9 – 99:1 d.r.	204
24		Arylation	ArI		Pd(OPiv) ₂ (10 mol%), Ag ₂ CO ₃ (1.5 equiv), (BnO) ₂ PO ₂ H (1.0 equiv), HFIP/DMSO (9:1) (1.0 mL), 120 °C, N ₂ , 12 h. R = Me: 11 examples with substituted iodobenzenes carrying OPiv, OCF ₃ , OMe, OTs, NHAC, Me, CF ₃ , Br, and COOMe substituents; 42-70% yield. R = (substituted) benzyl or alkyl: 8 examples, 37-68%.	201
25		Arylation	ArI		Pd(OPiv) ₂ (10 mol%), Ag ₂ CO ₃ (1.5 equiv), (BnO) ₂ PO ₂ H (1.0 equiv), HFIP/DMSO (9:1) (1.0 mL), 90 °C, N ₂ , 12 h. R = Ph or 4-BrC ₆ H ₄ ; Ar = phenyl, 4-MeOC ₆ H ₄ , or 4-BrC ₆ H ₄ ; 3 examples, 50-66%, 88:12 – 90:10 d.r.	201
26		Alkylation - Amination			Substrate (0.10 mmol), malonate (0.2 mmol), Cu(OAc) ₂ (20 mol%), Li ₂ CO ₃ (0.1 mmol), Ag ₂ CO ₃ (0.15 mmol), DMSO (4.0 mL), air, 80 °C, 12 h. R ¹ = H, Me, <i>t</i> Bu, MeO, F, Cl, Br, I, Ac, CF ₃ , Ph, CH ₂ =CH; 20 examples, 40-72%. C–H cleavage could potentially be the rate-limiting step	208
27		Arylation	Ar-Br		Substrate (0.5 mmol), PhBr (0.6 mmol), [RuCl ₂ (η ⁶ -C ₆ H ₆) ₂] (0.0125 mmol), PPh ₃ (0.05mmol), K ₂ CO ₃ (1.0 - 2.0 mmol), NMP (1 mL), 120 °C, N ₂ , 20 h. DG = Oxazole: R = Me, 1 example, 66% DG = Benzoxazole: Bisarylation occurred (R = Ph), Single example, 55%	157

28		Fluorination	NFSI		Substrate (1 equiv), NFSI (1.5 equiv), Pd(OAc) ₂ (10 mol%), TFA (2 equiv), and a mixed solvent (CH ₃ NO ₂ / CH ₃ CN, 2.0 mL), sealed tube, air, 110 °C R = H (64%), Cl (35%), OMe (53%)	214
29		Acylation			Substrate (0.4 mmol), aldehyde (2.4 mmol), Pd(OAc) ₂ (5 mol%), PPh ₃ (10 mol%), TBHP (2.4 mmol), PhCl (2.0 mL), reflux, 8 h. R ¹ = H, Br, Cl, F, Me, MeO; R ² = H, Cl, F, Me, MeO; 17 examples, 39-85%. Also benzothiazole and benzo[h]quinolone was used as DG successfully, benzimidazole gave no conversion.	209
30		Acylation			Substrate (0.4 mmol), aldehyde (2.4 mmol), Pd(OAc) ₂ (5 mol%), PPh ₃ (10 mol%), TBHP (2.4 mmol), PhCl (2.0 mL), reflux, 8 h. R ¹ = H, OMe, Cl; 3 examples, 42-81%. Also benzothiazole and benzo[h]quinolone was used as DG successfully, benzimidazole gave no conversion.	209
31		Acylation			Substrate (0.4 mmol), aldehyde (2.4 mmol), Pd(OAc) ₂ (5 mol%), PPh ₃ (10 mol%), TBHP (2.4 mmol), PhCl (2.0 mL), reflux, 8 h. R ¹ = H, Br, Cl; 3 examples, 37-55%. Also benzothiazole and benzo[h]quinolone was used as DG successfully, benzimidazole gave no conversion.	209
32		Arylation	[Ph ₂ I]BF ₄		Substrate (1 equiv), [Ph ₂ I]BF ₄ (1.1 – 2.5 equiv), Pd(OAc) ₂ (5 mol%), NaHCO ₃ (1.5 - 2.0 equiv), benzene, 100 °C, 12 h. Single example, 83%	215

33		Alkylation	R-I		Substrate (1 equiv), R-I (3 equiv), Pd(OAc) ₂ (10 mol%), AgOAc (2 equiv), toluene, air, 80 °C, 24 h; R ¹ = Me, Et, <i>Or</i> Bu; 4 examples, 73-91%.	¹⁹⁹
34		Arylation	Ar-I		Substrate (1 equiv), Ar-I (3 equiv), Pd(OAc) ₂ (10 mol%), AgOAc (2 equiv), toluene, air, 80 °C, 24 h; R ¹ = H, Me, Et, <i>Or</i> Bu; 4 examples, R ² = Me, OMe, COMe, F, Cl, Br, I, NO ₂ , CF ₃ , B(OR) ₂ , N ₃ ; 16 examples, 61-93%.	¹⁹⁹
35		Iodination	NIS		Pd(OAc) ₂ (5 mol%), NIS (1.05 equiv), 100-120 °C, 12 h, MeCN or AcOH. 1 example, 54%	¹⁶⁰
36		Amidation			Substrate (1 equiv), dioxazolone (1.2 equiv), Cp*Co(CO)I ₂ (5 mol%), AgSbF ₆ (20 mol%), NaOAc (20 mol%), DCE, 100 °C, 20 h. 2 examples: R ¹ = 3-F (71%), 4-Me (66%)	¹⁵
37		Carbonylation	CO, CH ₂ =CH ₂		5 mol% Ru ₃ (CO) ₁₂ , ethylene, CO, 20 atm, toluene, 160 °C single example, 37%.	¹⁹⁶

Heterocyclic and related directing groups in C-H activation chemistry

Imidazole derivatives are rarely applied as DGs, since the imidazole ring system is relatively prone to C-H insertions itself. One example has been reported by Kakiuchi and coworkers in their well-known ruthenium catalyzed silylation protocol (Table 8, Entry 2).¹⁶¹

Here, amongst series of other heterocyclic DGs, also one example using a imidazole derivative was reported. Another single example in a larger study came from the lab of Inoue. *N*-Methylimidazole proved to be efficient in promoting only mono-arylation, whereas other heterocyclic DGs often also gave bis-arylation (Table 8, Entry 3).¹⁵⁷ Most likely, the *N*-methyl group prevents free rotation around the phenyl-DG bond and the second ortho position cannot be activated anymore.

Thiazole compared to other heterocycles, is underrepresented as DG. Reasons are again that thiazole can be C-H activated itself, primarily in positions 2 and 5. Hence, conditions in which thiazole is applied as DG need to leave the thiazole C-H bonds untouched. The Ru-catalyzed arylation protocol reported by Inoue and coworkers is such an example (Table 8, Entry 3).¹⁵⁷ In order to get selective mono-arylation of arenes, one *ortho* position had to be blocked in advanced, otherwise mixtures of mono- and bis-arylation were obtained. Taking such precautions, the reaction was generally high yielding (up to 98%).

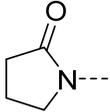
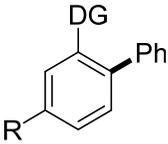
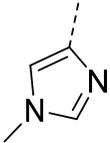
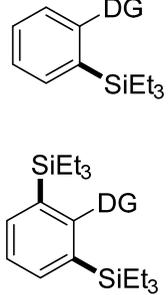
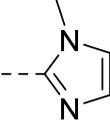
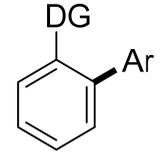
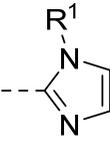
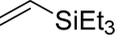
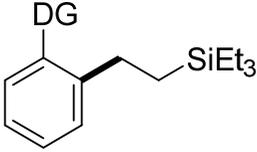
Already in 2000 Murai and coworkers¹⁹⁶ reported one example of thiazoline as DG in a carbonylation reaction with CO and ethylene (Table 8, Entry 7).

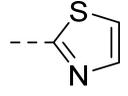
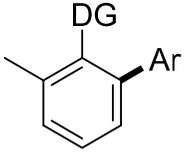
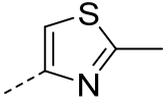
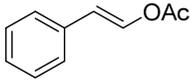
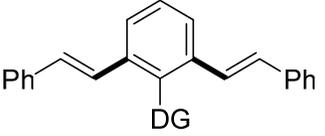
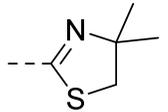
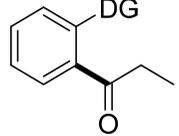
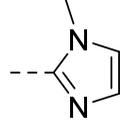
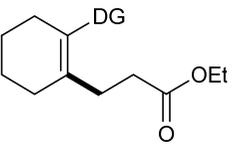
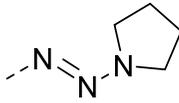
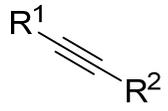
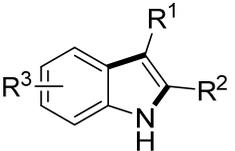
The triazene motif was used as ‘internally cleavable’ directing group in the synthesis of free indoles by Sun et al.²¹⁶ The so formed indole derivatives could be further transformed to the corresponding indolo[2,1-*a*]isoquinolines in a 2-step one pot set up (Table 8, Entry 9 & 10). The process is believed to be a triple C-H/N-H/C-H activation cascade. Ghorai and Chouhury²¹⁷ showed the application of an *N*-heterocyclic carbene (NHC) as directing group in an intermolecular C-H activation / annulation reaction employing various alkynes as reaction partners. To the best of our knowledge, this represents the only example in the literature where NHCs are used as directing groups rather than as ligands. 7-Azaindoles have been investigated concerning their potential applicability in C-H activation by Qian et al. (Table 8, Entry 13)²¹⁸ The attempted chlorination using dichloroethane as halogen-source proceeded smoothly and according to the mechanism proposed, the directing effect is attributed to the pyridine –nitrogen. Phenidones (Table 8, Entry 12) have been selectively *ortho*-aminated by Xue et al.²¹⁹ The phenindone motif is readily transformed to other heterocyclic compounds.

In 2015 the group of Zhang presented pyridazinone as DG, which can be used for different direct transformations, like the Pd(II) promoted arylation with aryl iodides or using benzaldehyde derivatives for a regioselective carboxylation. Additionally, the pre-catalyst [RhCp*Cl₂]₂ was used for olefination or naphthylation using diphenylethyne under the same reaction conditions.²¹

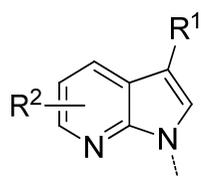
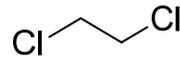
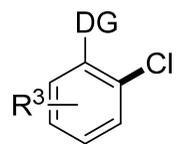
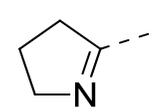
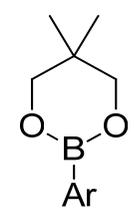
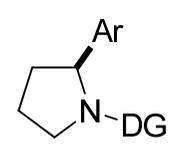
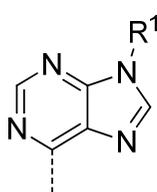
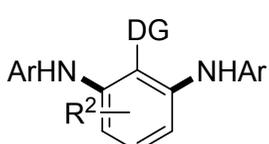
An monoselective alkenylation protocol established for 2-aryl-1,3-dithiane derivatives catalyzed by a Rh(III) complex was reported by Unoh et al. This rarely known directing group can be directly removed after the C-H functionalisation by the Dess–Martin periodinane reagent in a MeCN/CH₂Cl₂/H₂O co-solvent system at room temperature resulting in deprotection to furnish aldehydes in an excellent yield. Another stated deprotection protocol including a reductive desulfurization and alkene reduction was achieved by treatment with Raney-Ni in EtOH, rt. for 6 h.²²⁰

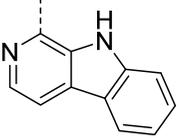
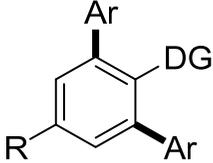
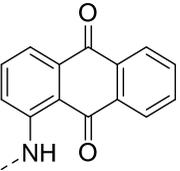
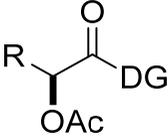
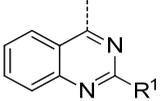
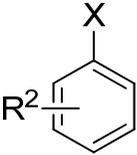
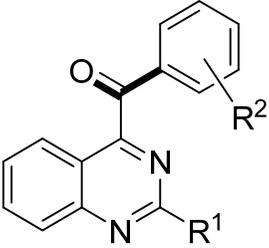
Table 8: Heterocyclic and related directing groups in C-H activation chemistry

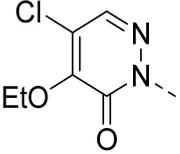
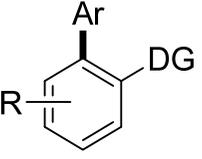
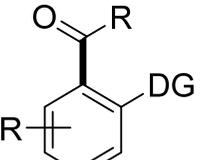
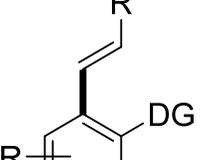
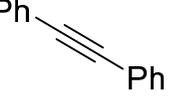
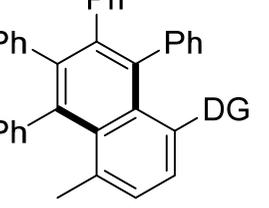
Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
1		Arylation	$[\text{Ph}_2\text{I}]\text{BF}_4$		Substrate (1 equiv), $[\text{Ph}_2\text{I}]\text{BF}_4$ (1.1 – 2.5 equiv), $\text{Pd}(\text{OAc})_2$ (5 mol%), NaHCO_3 (1.5 - 2.0 equiv), toluene, 100 °C, 12 – 24 h. 3 examples, R = H (75%), OMe (84%), Br (78%).	215
2		Silylation	HSiEt_3		Substrate (1 mmol), HSiEt_3 (5 mmol), norbornene (5 mmol), $\text{Ru}_3(\text{CO})_{12}$ (6 mol%), toluene (0.5 ml), reflux, 20h Single example, 13% mono silylation, 56% bis silylation	161
3		Arylation	Ar-Br		Substrate (0.5 mmol), PhBr (0.6 mmol), $[\text{RuCl}_2(\eta^6\text{-C}_6\text{H}_6)]_2$ (0.0125 mmol), PPh_3 (0.05mmol), K_2CO_3 (1.0 - 2.0 mmol), NMP (1 mL), 120 °C, N_2 , 20 h. Ar = Ph (84%), Ar = 3-thienyl (83%).	157
4		Alkylation			Substrate (1 equiv), alkene (3 equiv), $[\text{RuCl}_2(\text{p-cymene})]_2$ (2.5 - 5 mol%), MesCOOK (30 mol%), toluene, 100 – 120 °C, 18 – 24 h. 2 examples, $\text{R}^1 = \text{H}$ (50%), Me (51%).	24

5		Arylation	Ar-Br		Substrate (0.5 mmol), PhBr (0.6 mmol), [RuCl ₂ (η ⁶ -C ₆ H ₆) ₂] (0.0125 mmol), PPh ₃ (0.05mmol), K ₂ CO ₃ (1.0 - 2.0 mmol), NMP (1 mL), 120 °C, N ₂ , 20 h. Ar substituents included H, Me, OMe, F, COMe; 8 examples, 63-98%	157
6		Alkenylation			Substrate (1 mmol), alkene source (3 mmol), 3 (0.05mmol), toluene (1.5 mL), reflux, 50 h. Single example, 60%	190
7		Carbonylation	CO, CH ₂ =CH ₂		5 mol% Ru ₃ (CO) ₁₂ , ethylene, CO, 20 atm, toluene, 160 °C Single example, 73%.	196
8		Alkylation/Alkenylation	Alkene/Alkyne		Olefin (1 equiv), unsaturated coupling partner (1 equiv), [ReBr(CO) ₃ (THF)] ₂ (2.5 mol%), toluene, 135 °C, 24 h 13 examples, yields generally above 50%	221
9		Synthesis of Indoles			Substrate (0.3 mmol), alkyne (1.1 equiv), [RhCp*Cl ₂] ₂ (5 mol%), AgSbF ₆ (20 mol%), Cu(OPiv) ₂ (2 equiv), MeOH/ ^t AmOH=1:1, 90 °C, under argon. 12 Examples; 47-93% R ¹ = Aryl, Alkyl R ² = Aryl R ³ = CN, COOMe, Ac, Br, OMe, NO ₂ , CH ₂ OH	216

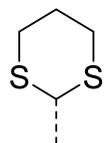
10		Synthesis of Indolo[2,1- <i>a</i>]isoquinolines			<p>Method A: Substrate (0.2 mmol), alkyne (3.5 equiv), [RhCp*Cl₂]₂ (5 mol%), AgSbF₆ (20 mol%), Cu(OPiv)₂ (2 equiv), MeOH/<i>n</i>-AmOH=1:1, 90°C, under argon.</p> <p>Method B: Substrate (0.2 mmol), alkyne (3.5 equiv), [RhCp*Cl₂]₂ (5 mol%), AgSbF₆ (20 mol%), Cu(OAc)₂·H₂O (2 equiv), DCE, 90°C, under argon.</p> <p>16 Examples; 35-79%</p> <p>R = Ac, halogen, OMe, CN, NO₂</p>	
11					<p>Substrate (0.1 mmol), reagent (0.12 mmol), [Cp*RhCl₂]₂ (5 mol-%), NaOAc (4 equiv), AgOTf (3 equiv), CH₂Cl₂ (3.0 mL), N₂ atm. rt., 24 h.</p> <p>16 Examples; 29-80% yield</p> <p>R¹ = Alkyl</p> <p>R² = OMe, NO₂</p> <p>R³ = Ph, COOMe, alkyl</p>	217
12		Amination			<p>Substrate (0.5 mmol), reagent (0.75 mmol), [Cp*RhCl₂]₂ (4 mol-%), CsOAc (2 equiv), PivOH (0.5 equiv) in toluene (2 mL) under air, 3-5 h.</p> <p>R¹ = Alkyl</p> <p>R² = Me, OMe, OCF₃, Br, NO₂</p>	219

13		Chlorination			<p>Substrate (0.3 mmol), Rh[Cp*Cl₂]₂ (2.0 mol%), Cu(TFA)₂ (2.0 equiv), ^tBuNC (2.0 equiv), Li₂CO₃ (1.0 equiv), DCE (1.5 mL), 130 °C, air, 23–53 h.</p> <p>31 Examples; 32-85% yield</p> <p>R¹ = Halogen, C(O)R, aryl</p> <p>R² = OMe, halogen, aryl, alkyl</p> <p>R³ = Halogen, OMe, Me, COOMe, C(O)Me, NO₂</p>	218
14		Arylation			<p>Substrate (1 mmol), coupling partner (1.2 equiv), ^tBuCOMe (5 equiv), Ru₃(CO)₁₂ (3.3 mol%), 150 °C, 4-19 h</p> <p>9 Examples, 38-76% yield</p>	1
15		Amination	N ₃ -Ar		<p>Condition A: Aryl azide (0.2 mmol), Substrate (2 equiv), [RhCp*Cl₂]₂ (2mol%), and AgSbF₆ (8 mol%) in ClCH₂-CH₂Cl for 12 h obtain mono substitution.</p> <p>Condition B: Substrate (0.2 mmol), aryl azide (3 equiv), [RhCp*Cl₂]₂ (4 mol%), and AgSbF₆ (16 mol%) for 24 h obtain double substitution.</p> <p>22 Examples; Yield: 58-95%</p> <p>R¹= Alkyl, Bn</p> <p>R²= Me, Cl, NO₂, OH, CF₃, CHO, COOMe, SO₂Me</p>	222

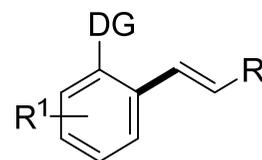
16		Arylation	ArBr		<p>Substrate (0.2 mmol), ArBr (0.5 mmol), [RuCl₂(<i>p</i>-cymene)]₂ (5.0 mol%), K₂CO₃ (0.5 mmol), Ph₂CHCO₂H (30 mol%), NMP, 120 °C, 20 h.</p> <p>Monoarylated product was observed in small amount.</p> <p>Mechanism was studied</p> <p>39 Examples; Yield: 40-92%</p> <p>R= Me, OMe, CN, F, NO₂</p> <p>Substituted ArBr: Bu, OMe, CN, NMe₂,</p> <p>Hetero-bromides tolerated</p>	223
17		Acetylation	PhI(OAc) ₂		<p>Substrate (0.1 mmol), Pd(OAc)₂ (0.1 equiv), PhI(OAc)₂ (5 equiv) and LiOAc (2 equiv) in DCE (0.5 mL) in a sealed tube at 120 °C for 12 h.</p> <p>Removal: NaOH (2 equiv), in MeOH, reflux, 10 min; released 1-amino anthraquinone can be reused.</p> <p>17 Examples; Yield: 0-92%</p> <p>R= Alkyl, cyclopentane, cyclohexane, aryl, vinyl, halogen</p>	40
18		Arylation oxidation			<p>Substrate (0.3 mmol), ArX (2 equiv), Pd(PPh₃)₄ (0.1 equiv), BINAP (0.1 equiv), Cs₂CO₃ (2 equiv), air, toluene (3mL), 100 °C.</p> <p>28 Examples, Yield: 0-79%</p> <p>R¹= Alkyl, Ph, Cy</p>	224

					$R^2 = \text{Me, OMe, halogen, NO}_2, \text{CF}_3, \text{CHO, COOMe}$ $X = \text{Cl, Br, I}$	
19	 (Pyridazinone)	Arylation	ArI		Substrate 0.1 mmol, reagent (10 equiv), AgOAc (1.5 equiv), Pd(OAc) ₂ (10 mol%). 18 Examples; Yield: 12-84% $R = \text{Alkyl, COOMe, OMe, halogen}$	21
20		Carboxylation	RCHO		Substrate (0.28 mmol), aldehyde (1.5 equiv), Pd(OAc) ₂ (10 mol%), TBHP (2 equiv), DCE, 80 °C, 5 h. 6 Examples; Yield: 60-90% $R = \text{substituted Ph, Cy, thiophene (Cl, NO}_2, \text{OMe)}$	
21		Olefination			Substrate (0.28 mmol), alkene (2 equiv), [RhCp*Cl ₂] ₂ (2.5 mol%), AgSbF ₆ (10 mol%), PivOH (2 equiv), Ag ₂ CO ₃ (2 equiv), MeOH, 100 °C, 2 h. 3 Examples; Yield: 91-96% $R = \text{COO}^n\text{Bn, CONH}_2, \text{Ph}$	
22		Naphthylation			Substrate (0.26 mmol), diphenylacetylene (2 equiv), [RhCp*Cl ₂] ₂ (2.5 mol%), AgSbF ₆ (10 mol%), Ag ₂ CO ₃ (2 equiv), PivOH (2 equiv), MeOH, 100 °C. 1 Examples; Yield: 89%	

23



Alkenylation



Substrate (0.25 mmol), reagent (0.5 mmol), [Cp*Rh-(MeCN)₃][SbF₆]₂ (0.02 mmol), Cu(OAc)₂·H₂O (0.5 mmol), in THF (2 mL) at 60 °C under N₂ for 24 h.

2 removal protocol: (1):- Dess–Martin periodinane reagent in a MeCN/CH₂Cl₂/H₂O co-solvent system at room temperature resulted in deprotection to furnish aldehydes in an excellent yield. (2):- reductive desulfurization/alkene reduction was archived by treatment with Raney-Ni in EtOH, rt. for 6 h.

27 Examples; Yield: 0-93%

R= COOⁿBu, COO^tBu

R¹= Me, alkoxy, MeS, NO₂, halogene, CF₃,

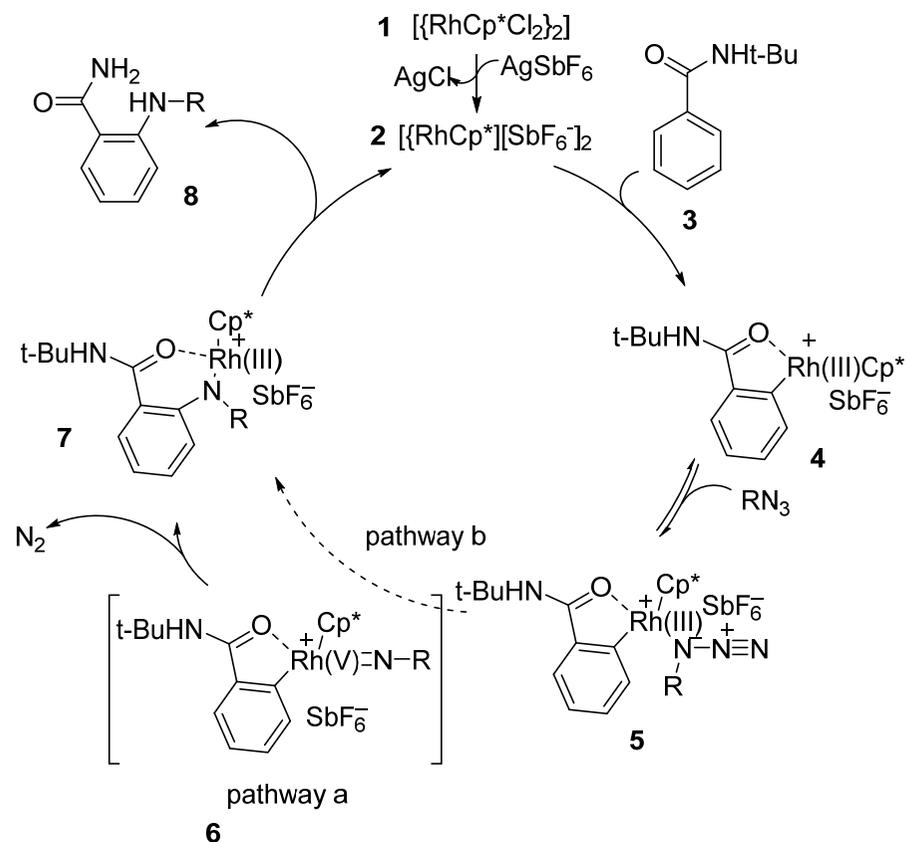
Heterocycles tolerated

220

Amides as directing groups

Substituted as well as unsubstituted amides proved to be extremely valuable as directing groups in C-H activation. The first example utilizing an unsubstituted amide (CONH₂) in C-H activation was presented by Li et al. in 2012 (Table 9, Entry 1).⁷⁷ Employing AcOH as solvent, facilitates the electrophilic attack of the Pd(II) catalyst to the benzamide coupling partner. Both, electron donating as well as electron withdrawing substituents were tolerated on both reaction partners and a variety of biphenyl-2-carboxamides could be prepared in synthetically useful yields of up to 84%. An extremely diverse set of amide-facilitated *ortho*-modifications is known in the literature amongst which not only arylation reactions are represented but also less classical amidation, amination and alkylation reactions. The Chang group presented the enormously functional group tolerant amination starting from *N*-*t*-butylbenzamide and an aryl azide as coupling partner (Scheme 5, Table 9, Entry 11).²²⁵ AgSbF₆ facilitates the ligand exchange in the catalytic system and thereby the formation of a five-membered rhodacyclic intermediate (**4**). The azide reaction partner coordinates to this intermediate and subsequent loss of N₂ via either pathway b or via formation of a nitrenoid **6** (pathway a) affords the Rh(III) amido species **7** which upon protonolysis delivers the *ortho*-*N*-functionalized aniline **8**.

The same group reported an extremely mild (the reaction is conducted at 45 °C) iridium-catalyzed arylation of benzamides with aryldiazonium tetrafluoroborates as coupling partners (Table 9, Entry 13).²²⁶ With this reaction conditions, also (*Z*)-selective arylation of enamides was accomplished in good yields (40-83%). In 2012 Sharma et al. presented the tandem *ortho*-acylation of *N*-*i*-propylbenzamides followed by intramolecular cyclization (Table 9, Entry 6).²²⁷ This Rh-catalyzed sequential process allowed for the elegant preparation of substituted 3-hydroxyisoindoles and was later developed further towards an enantioselective transformation utilizing an iridium-based catalyst and a chiral bidentate phosphoramidite ligand^{228, 229} employing *N,N*-dimethylamide as directing group (Table 9, Entry 17).



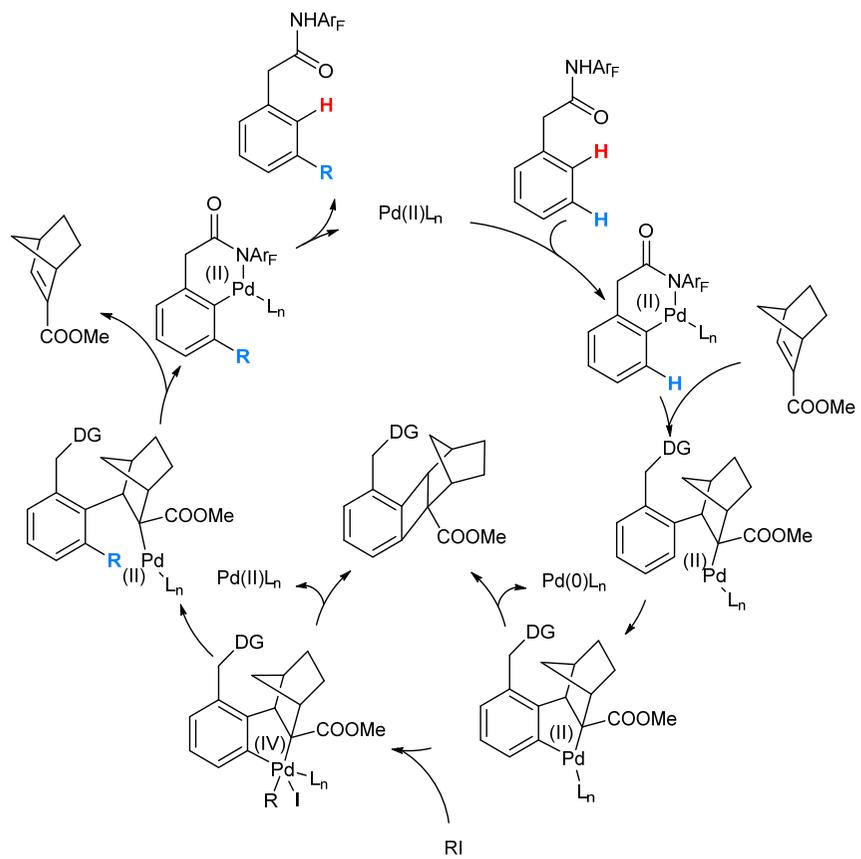
Scheme 5: Proposed mechanism of the Rh-catalyzed amination of *t*-Bu-benzamides.

The disubstituted *N,N*-diethylamide was successfully applied in the meta-selective borylation of aromatic substrates (Table 9, Entry 19).²³⁰ Although this reactivity was not exclusively shown for the *N,N*-diethylamide (OMOM, SONEt₂ and OCONEt₂ could also be applied to the reaction conditions), this unique meta-selectivity should be mentioned here. The investigated sequential meta-borylation, Suzuki-coupling is perfectly complementary to directed *ortho*-metalation and Suzuki coupling or an *ortho* functionalization via directed C-H activation. The transformation shows a good functional group tolerance and the meta-selectivity seems to be driven by steric influences rather than electronic effects. A Rh-catalyzed protocol for the *Z*-selective α -halogenation of alkenes was presented by the Glorius group (Table 9, Entry 27).²³¹ Haloacrylamides could be prepared using NXS as the halogen source which in most cases gave the best yields as NIS. The relatively mild conditions (60 °C) gave rise to a broad functional group tolerance allowing the reaction to proceed also in the presence of *p*- or *m*-bromine bringing about attractive synthetic intermediates.

The Glorius group utilized *N,N*-di-*i*-propylamide as directing group in the synthesis of the synthetically challenging [3]dendralene-motif.²³² Allenyl carbinol carbonates were used as reaction partner allowing for the installation of this motif on aromatic as well as olefinic starting materials under mild conditions with excellent functional group tolerance (Table 9, Entry 23).

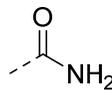
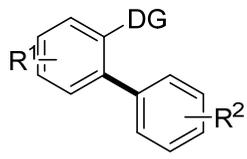
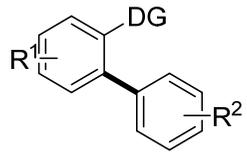
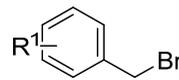
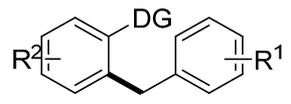
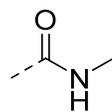
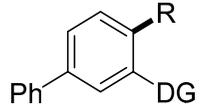
Amongst aromatic amides, many serve for the alpha selective functionalization of sp³- carbon centers. The enantioselective arylation of very congested cyclobutane is a particularly interesting example (Table 9, Entry 39).²³³ The highly electron deficient *N*-(4-cyano-2,3,5,6-tetrafluorophenyl)amide in combination with a modified amino acid as chiral ligand enables the Pd-catalyzed alpha functionalization in good yields and high ees.

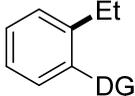
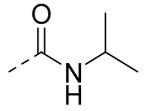
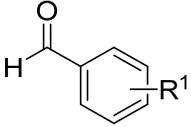
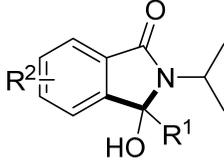
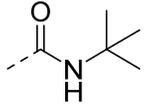
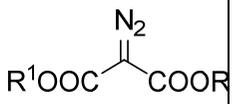
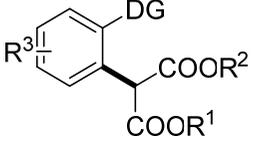
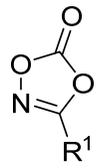
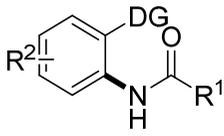
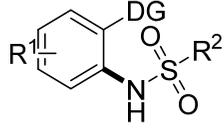
The very often challenging *meta*-modification of aromatic substrates was accomplished utilizing a modified norbornene which temporarily blocks the ortho position of the aromatic substrate thereby allowing for selective *meta* substitution with aryl- or alkyl iodides (Scheme 6). The relatively mild reaction conditions allow for a broad functional group tolerance and generally high yields. A second example for the rare meta functionalization was presented by the Yu group.²³⁴ A U-shaped weakly coordinating fully functionalized amide-directing group enables the highly selective meta arylation (Table 9, Entry 40)²³⁴ and olefination²³⁵ of substituted and unsubstituted aromatic substrates. The immensely bulky amide totally shields the ortho position and can be cleaved at room temperature.

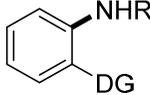
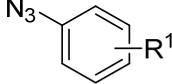
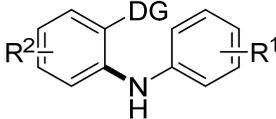
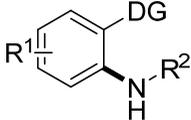
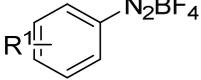
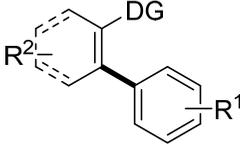


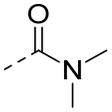
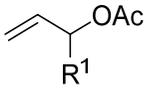
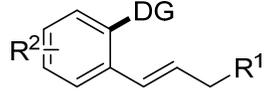
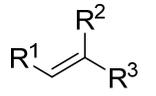
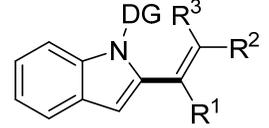
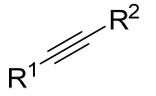
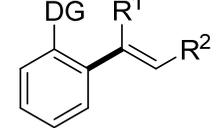
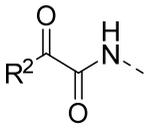
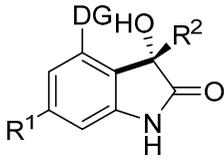
Scheme 6: *Meta*-selective functionalization; Proposed mechanism.

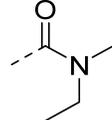
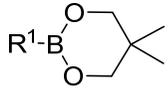
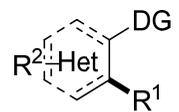
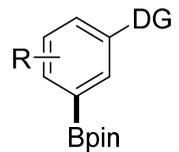
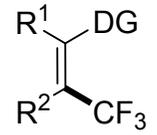
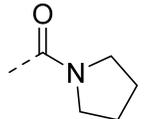
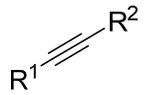
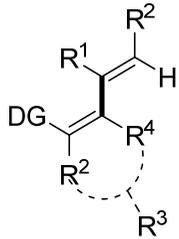
Table 9: Amide- directing groups in C-H activation chemistry

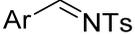
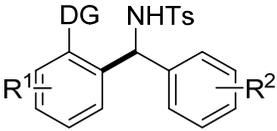
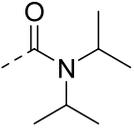
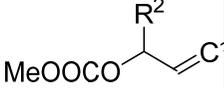
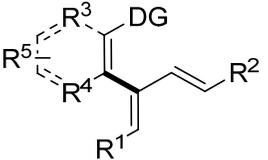
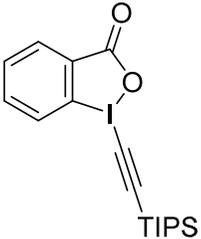
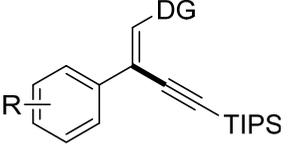
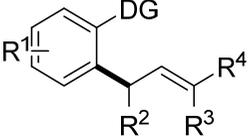
Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
1		Arylation	ArI		Substrate (0.5 mmol), aryl iodide (1 mmol), Pd(OAc) ₂ (0.025 mmol), Ag ₂ O (1 mmol), AcOH (5 mL), 120 °C, 5-24 h 23 Examples; Yield: 33-84% with max. 9% diarylated byproduct R ¹ = Me, OMe, Halogen, NO ₂ R ² = Me, OMe, Cl First example with unsubstituted amide	77
2		Arylation	ArI		Substrate (0.5 mmol), iodobenzene (1 mmol), PS-3 catalyst (15 mg), AgOAc (0.75 mmol), acetic acid (5 mL), 120 °C, 15-30 h 15 Examples, Yield: 36-74% R ¹ = Halogen, Me, OMe R ² = Me, OMe, C(O)Me Novel catalyst system; Pd/ mesoporous silica	236
3		Benylation			Substrate (0.2 mmol), benzylbromide (0.2 mmol), Pd(OAc) ₂ (5 mol%), PPh ₃ (10 mol%), Cs ₂ CO ₃ (0.24 mmol), dioxane (500 mM), 110 °C, 18 h 18 Examples; Yield: generally above 50% R ¹ = Me, OMe, CF ₃ , F R ² = OMe, Br, CF ₃	237
4		Alkylation	RCl		Substrate (1 equiv), alkyl chloride (1.2 equiv), Co(acac) ₂ (10 mol%), CyMgCl (3 equiv), DMPU (12 equiv), Et ₂ O, rt, 12 h 7 Examples; Yield: 15-73% R = Alkyl	238

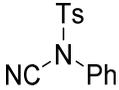
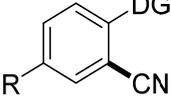
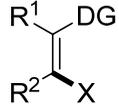
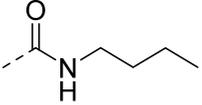
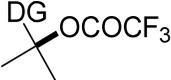
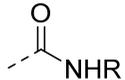
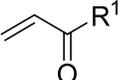
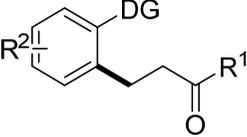
5		Alkylation	EtMgCl		Substrate (1 equiv), Co(acac) ₂ (10 mol%), EtMgCl (5.8 equiv), DMPU (30 equiv), air, THF, 25 °C, 12 h Yield: 79%	239
6		Acylation / Intramolecular Cyclization			Substrate (0.3 mmol), aldehyde (0.6 mmol), [Cp*RhCl ₂] ₂ (5 mol%), AgSbF ₆ (20 mol%), Ag ₂ CO ₃ (0.9 mmol), THF (1 mL), 150 °C, 20 h, N ₂ , pressure tube 22 Examples; Yield: 30-83% R ¹ = CF ₃ , COOMe, NO ₂ , C(O)Me, CN, Halogen, OMe R ² = Ph, OR, halogen	227
7		Alkylation			Substrate (0.2 mmol), diazomalonate (1.2 equiv), [IrCp*Cl ₂] ₂ (2 mol%), AgNTf ₂ (8 mol%), AgOAc (4 mol%), DCE (1 mL), 90 °C, 10 h 14 Examples; Yield: generally above 50% R ¹ = Me R ² = Me, ^t Bu, Bn R ³ = Halogen, Me, OMe; heterocycles tolerated	14
8		Amidation			Substrate (0.2 mmol), dioxazolone (1.1 equiv), [Cp*CoCl ₂] ₂ (1 mol%), AgSbF ₆ (4 mol%), NaOAc (6 mol%), DCE (0.5 mL), 80 °C, 24h 7 Examples; Yield: 60-83% R ¹ = Ph, Alkyl R ² = Me, CF ₃ , Halogen, OMe Also pyridine and benzamide applicable to reaction conditions	240
9		Amidation	sulfonyl azide		Substrate (0.2 mmol), sulfonyl azide (1.1 equiv), [IrCp*Cl ₂] ₂ (2 mol%), AgNTf ₂ (8 mol%), DCE (0.5 mL), 50 °C, 12 h 24 Examples; Yield: generally above 60%	241

					$R^1 = \text{Me, OMe, CF}_3, \text{NO}_2, \text{halogen, COOMe, CH}_2\text{OR}$ $R^2 = \text{Aryl, alkyl}$	
10		Amination	N_3R		Substrate (0.25 mmol), azide (0.35 mmol), $[\text{Cp}^*\text{MCl}_2]_2$ (4 mol%), AgSbF_6 (0.04 mmol), TCE (0.5 mL), 1.5 h; M = Ir, Rh, Co 4 Examples; Yield: 1- 95% depending on the metal used $R = \text{Tosyl, Bn, aryl, C(O)Ar}$ orthogonal reactivity between metal and azide	242
11		Amination			Substrate (0.36 mmol), azide (0.2 mmol), $[\text{RhCp}^*\text{Cl}_2]_2$ (2.5 mol%), AgSbF_6 (10 mol%), DCE (0.5 mL), 85 °C, 18 h 19 Examples; Yield: 45-97% $R^1 = \text{NO}_2, \text{CF}_3, \text{SO}_2\text{Me, COOR, C(O)Me, Cl}$ $R^2 = \text{OMe, Me, COOMe, Halogen, CH}_2\text{OH, CH}_2\text{OAc}$	225
12		Amination	N_3R^2		Substrate (0.2 mmol), azide (0.4 mmol), $[\text{RhCp}^*\text{Cl}_2]_2$ (4 mol%), AgSbF_6 (16 mol%), DCE (0.5 mL), 110 °C, 24 h 25 Examples; Yield: 45-94% $R^1 = \text{NO}_2, \text{OMe, Me, Halogen, CHO, CH}_2\text{OAc}$ $R^2 = \text{Alkyl, Aryl}$	243, 244
13		Arylation			Substrate (0.3 mmol), aryldiazonium salt (0.2 mmol), $[\text{IrCp}^*\text{Cl}_2]_2$ (5 mol%), AgBF_4 (20 mol%), NaOAc 30 mol%), $\text{CF}_3\text{CH}_2\text{OH}$ (1 mL), 35 °C, 12 h 21 Examples; Yield: 43-82% $R^1 = \text{Halogen, CF}_3, \text{Me, C(O)Me, COOMe}$; F, Cl and Br tolerated $R^2 = \text{Me, OMe, CF}_3, \text{Br, OAc,}$	226

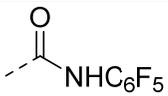
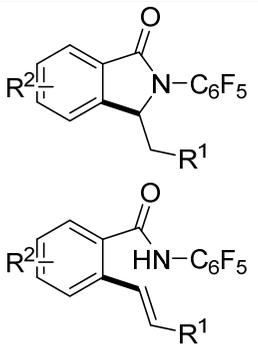
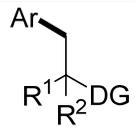
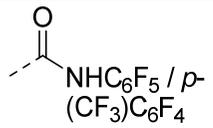
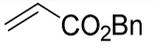
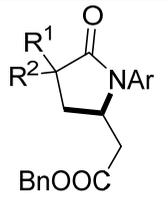
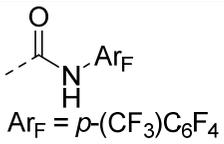
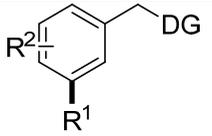
14		Alkenylation			Substrate (0.2 mmol), alkene (0.24 mmol), [Cp*RhCl2]2 (0.0025 mmol), AgSbF6 (0.01 mmol), DCE (1 mL), 16 h 22 Examples; Yield: generally above 50% R ¹ = Alkyl, aryl R ² = Me, OMe, TMS, CF ₃ , Ph, OH, halogen, COOR, C(O)R With R ¹ other than H, mixtures of isomers are formed	245
15		Alkenylation			Substrate (1 equiv), alkene (2 equiv), [Ru(<i>p</i> -cymene)Cl2]2 (2.5 mol%), AgSbF ₆ (10 mol%), Cu(OAc) ₂ ·H ₂ O (1 equiv), dioxane (0.15 M), 100 °C, 24 h 25 Examples; Yield: generally above 50%, R ¹ = Alkyl, Ph R ² = Alkyl R ³ = Aryl, COOR, SO ₂ Ph, PO(OEt) ₂ , CN Applicable also to monosubstitution of pyrrole Electron rich reaction partners generally preferred	246
16		Alkenylation			Substrate (0.25 mmol), alkyne (0.5 mmol), [RuCl2(<i>p</i> -cymene)]2 (0.0.125 mmol), AgSbF ₆ (0.05 mmol), AcOH (1 mmol), dioxane (3 mL), 100 °C, 5 h, N ₂ 8 Examples; Yield: 19-47% R ¹ = Me, Bu, Ph, H R ² = Ph, Si ^t Pr ₃	247, 248
17		Asymmetric Intramolecular Direct Hydroarylation			Substrate (0.25 mmol), [Ir(cod) ₂](BAR ^F ₄) (5 mol%), (<i>R,R</i>)-Me-BIPAM (1.1 equiv), DMF (1 mL), 135 °C, 16 h 24 Examples; Yield: 66-99% ee typically >90% R ¹ = Me, CF ₃ , Cl R ² = Aryl, alkyl	228, 229

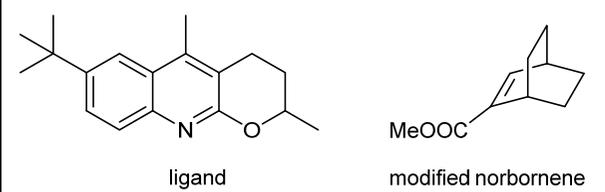
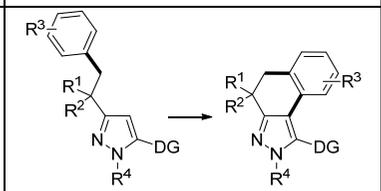
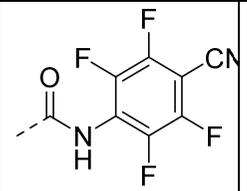
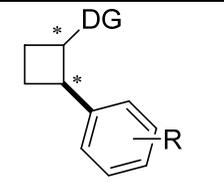
18		Arylation			<p>Substrate (1 equiv), ArBneop (1.5 equiv), $\text{RuH}_2(\text{CO})(\text{PPh}_3)_3$ (4 mol%), toluene, 125-135 °C, 24-44 h</p> <p>18 Examples; Yield: 18-90%</p> <p>R^1 = Aryl, heteroaryl</p> <p>R^2 = Alkyl, Ph, OMe</p> <p>Het = O, N, S</p>	249
19		Borylation	B_2pin_2		<p>Substrate (1 equiv), $[\text{Ir}(\text{cod})(\text{OMe})_2]_2$ (2 mol%), dtbpy (4 mol%), B_2pin_2 (0.6 equiv), hexanes, 80 °C, 18 h</p> <p>8 Examples; Yield: 32-86%</p> <p>R = TMS, halogen, OMe,</p> <p>Substitution in meta position</p> <p>If a <i>o</i>-TMS is present, substitution in para position</p>	250
20		Trifluoromethylation			<p>Substrate (0.3 mmol), CuI (1.1 equiv), TFA (10 equiv), <i>n</i>-methylformamide (15 equiv), DCE (9 mL), air, 120 °C, 16 h</p> <p>8 Examples; Yield: 11 – 69%</p> <p>R^1 = Aryl, ^{<i>n</i>}Bu</p> <p>R^2 = Ph, H</p>	250
21		Alkenylation			<p>Substrate (0.5 mmol), alkyne (0.55 mmol), $[\text{Rh}(\text{cod})_2]\text{BF}_4/\text{BIPHEP}$ (0.05 mmol), DCM (1 mL), 25 °C, 18-72 h</p> <p>15 Examples; Yield: 20-93%</p> <p>R^1, R^2 = Alkyne, aryl, alkyl</p> <p>R^3 = OMe, CF_3</p> <p>R^2, R^4 = Me, $-(\text{CH}_2)_4-$</p> <p>Very good <i>E</i>-selectivity</p>	251

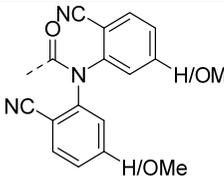
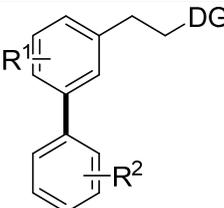
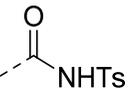
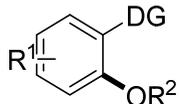
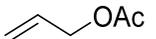
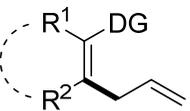
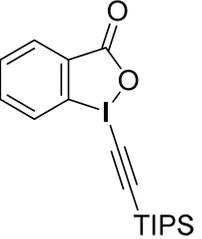
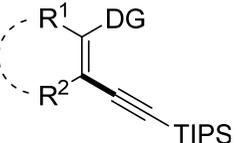
22		Amination			<p>Substrate (1 equiv), tosylimine (1.5 equiv), [Cp*RhCl_2]₂ (2.5 mol%), AgB(C₆F₅)₄ (10 mol%), DCE (0.75 M), 75 °C, 20 h</p> <p>16 Examples; Yield: 36-94%</p> <p>R¹ = OMe, CF₃, C(O)Me, Br, Me</p> <p>R² = NO₂, COOMe, CF₃, CN, halogen, Me; thiophene tolerated</p>	252
23		Alkenylation			<p>Substrate (0.4 mmol), allenyl carbinol carbonate (0.8 mmol), [Cp*$\text{Rh}(\text{MeCN})_3$](SbF₆)₂ (5 mol%), Cu(OAc)₂ (15 mol%), PivOH (1 equiv), DCM (2 mL), 60 °C, 3-24 h</p> <p>27 Examples; Yield: 30-87%</p> <p>R¹ = Alkyl</p> <p>R² = Alkyl, Ph</p> <p>R³ = CH; Ph, Me</p> <p>R⁴ = CH; Aryl, Br, COOEt</p> <p>R⁵ = CF₃, halogen, Me, CHO, OMe, COOMe</p>	252
24		Alkynylation			<p>Substrate (0.2 mmol), hypervalent alkynyl iodine reagent (2 equiv), RhCp*(MeCN)₃(SbF₆)₂ (10 mol%), DCM (1.5 mL), 80 °C, 16 h</p> <p>9 Examples; Yield: 38-92%</p> <p>R = OMe, NO₂, Halogen, Me</p> <p><i>ortho</i> alkynylation of benzamides also possible</p>	253
25		Allylation	allyl carbonate		<p>Substrate (0.4 mmol), allyl carbonate (0.8 mmol), [²⁵⁴Ir] (2.5 mol%), AgSbF₆ (30 mol%), PivOH (1 equiv), PhCl (2 mL), 35-50 °C, 18 h</p> <p>20 Examples; Yield: 42-84%</p> <p>R¹ = Me, OMe, Br, CHO, COOMe, CF₃</p> <p>R² = R³ = -(CH₂)₃-</p>	255

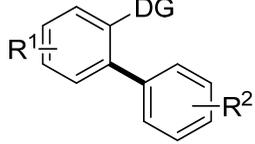
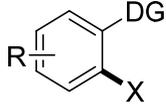
					$R_2 = H$ $R_3 = R_4 = Me$ Alkylation of electron-neutral arenes	
26		Cyanation			Substrate (0.5 mmol), <i>N</i> -cyano- <i>N</i> -phenyl- <i>p</i> -toluenesulfonamide (1 mmol), [RuCl ₂ (<i>p</i> -cymene)] ₂ (5 mol%), AgSbF ₆ (20 mol%), NaOAc (20 mol%), DCE (2 mL), 120 °C, 24 h 15 Examples; Yield: generally above 50% R = Me, OMe, COOMe, Ph, halogen; thiophene, furan and indole applicable	93
27		Halogenation	NXS X = I, Br		Substrate (0.4 mmol), NXS (1.1 equiv), [RhCp*Cl ₂] ₂ (2.5 mol%), AgSbF ₆ (10 mol%), PivOH (1.1 equiv), DCE, 60 °C, 16 h 23 Examples; Yield: 39-93% R ¹ = Alkyl, Ph, Br R ² = Aryl, Me Z selective	231
28		β-Acyloxylation	CF ₃ COOH		Substrate (1 mmol), CF ₃ COOH (5 mmol), Pd(OAc) ₂ (0.1 mmol), K ₂ S ₂ O ₈ (2 mmol), 80 °C, 20 h 1 Example, 91%	256
29		Alkylation			Substrate (0.5 mmol), alkene (1 mmol), [RuCl ₂ (<i>p</i> -cymene)] ₂ (5 mol%), KO ₂ CMes (30 mol%), MesCO ₂ H (1 equiv), H ₂ O, N ₂ , 120 °C, 20 h 20 Examples; Yield: 45-81% R ¹ = Alkyl R ² = Halogen, OMe, CF ₃ , Ph Combination with oxidative alkene annulation towards	257

					chinolin derivatives also reportet	
30		Alkylation			Substrate(0.4 mmol), alkene (2 equiv), [Cp*CoI ₂] ₂ (2.5 mol%), AgBF ₄ (40 mol%), AcOH (40 mol%), TFE, 60 °C, 16 h 18 Examples; Yield: 22-81% R = Alkyl, Bn, OMe, NO ₂ , halogen Also alkenylamides as substrates applicable	258
31		Intramolecular Annulation			Substrate (0.25 mmol), [RhCp*Cl ₂] ₂ (2.5 mol%), Cu(OAc) ₂ (0.5 mmol), <i>t</i> -AmOH (2 mL), 110 °C 20 Examples; Yield: generally above 60% R ¹ = Aryl, Me R ² = OMe, CF ₃ , Br R ¹ cannot be H	259
32		Heteroarylation	Heteroarene		Substrate (0.2 mmol), heteroarene (0.6 mmol), [RhCp*Cl ₂] ₂ (1.5 mol%), Cu(OAc) ₂ (2 equiv), K ₂ HPO ₄ (1.5 equiv), dioxane (1 mL), 130 °C, 24 h, N ₂ 25 Examples; Yield: 35-91% R ¹ = Halogen, OMe R ² = Alkyl, halogen, COOEt, CN X = S, O Many alternatives to <i>N</i> -Ph investigated with generally very bad yields	260
33		Alkenylation			Substrate (0.3 mmol), olefin (0.6 mmol), [RhCp*Cl ₂] ₂ (2.5 mol%), AgSbF ₆ (10 mol%), Cu(OAc) ₂ ·H ₂ O (200 mol%), <i>t</i> -AmOH, 100 °C, 20 h 23 Examples; Yield: 25-84% R ¹ = COOR, SO ₂ Ph, PO(OEt) ₂ , CONMe ₂	261

					$R^2 = \text{OMe, NO}_2, \text{CN, halogen, Me}$	
34		Alkenylation			Substrate (0.2 mmol), alkene (0.5 mmol), $[\text{RhCp}^*\text{Cl}_2]_2$ (0.01 mmol), NaOPiv (0.2 mmol), MeCN (2 mL), air, 80 °C, 24 h 25 Examples; Yield: generally above 50% $R^1 = \text{Aryl, COOR, CN}$ $R^2 = \text{Me, OAc, halogen, C(O)Me}$ If $R^1 = \text{Aryl}$, no cyclization occurs	262
35		Arylation	ArI		Substrate (0.2 mmol), aryl iodide (3 equiv), Pd(OAc)_2 (10 mol%), ligand (20 mol%), CsF (3 equiv), 3 Å MS (100 mg), toluene (1 mL), 100 °C, N_2 , 24 h 11 Examples; Yield: 30-84% (yield of mono-arylated product) $R^1 = \text{Me, H}$ $R^2 = \text{Alkyl, aryl}$	263, 264
36		Alkenylation / Intramolecular Cyclisation			Substrate (0.2 mmol), benzyl acrylate (0.1 mL), Pd(OAc)_2 (10 mol%), LiCl (2 equiv), Cu(OAc)_2 (1.1 equiv), AgOAc (1.1 equiv), DMF (1 mL), 120 °C, N_2 , 12 h 16 Examples; Yield: 18-94% $R^1 = \text{Me, H}$ $R^2 = \text{Alkyl, CH}_2\text{OR, CH}_2\text{COOR, Bn}$ $\beta\text{-C-H}$ alkenylation followed by 1,4-conjugate addition towards lactam	265
37		Alkylation / Arylation	$R^1\text{I}$		Substrate (0.1 mmol), iodoarene (3 equiv), Pd(OAc)_2 (10 mol%), ligand (20 mol%), norbornene (3 equiv), AgOAc (3 equiv), PhCF_3 (1.5 mL), 90 °C, air, 24 h 8 Examples; Yield: 57-87% yield	266, 267

					<p>R^1 = Alkyl, aryl R^2 = OMe, halogen, alkyl</p> <p>Substrate (0.1 mmol), alkyl iodide (2.5 equiv), Pd(OAc)₂ (10 mol%), ligand (10 mol%), norbornene (1.5 equiv), AgOAc (3 equiv), DCE (1.5 mL), 75 °C, air, 16 h</p> <p>31 examples, 52-90% yield</p> <p>R^1 = Alkyl, aryl R^2 = OMe, halogen, alkyl</p>  <p>ligand modified norbornene</p> <p><i>meta</i> directing</p>	
38		Arylation (dual)	ArI	 <p>Substrate (0.05 mmol), iodoarene (0.15 mmol), Pd(OTf)₂(MeCN)₄ (10 mol%), Ag₂O (0.1 mmol), AcOH (0.5 mL), 120 °C, 24 h</p> <p>27 Examples; Yield: 32-83%</p> <p>R^1 = Alkyl R^2 = Me R^3 = Me, Ph, halogen, PO(OEt)₂, COOMe, OMe R^4 = Alkyl</p>	268	
39		Arylation	ArBPIn	 <p>Substrate (0.1 mmol), ArBPIn (2 equiv), Pd(OAc)₂ (10 mol%), chiral ligand (11 mol%), Ag₂CO₃ (2.5 equiv), Na₂CO₃ (2 equiv), BQ (0.5 equiv), H₂O (5 equiv), <i>t</i>-amylOH (0.5 mL), N₂, 70 °C, 24 h</p> <p>18 Examples; Yield: generally above 50%, > 84% ee</p> <p>R = Me, Halogen, OMe, NHAc, COOR</p>	233	

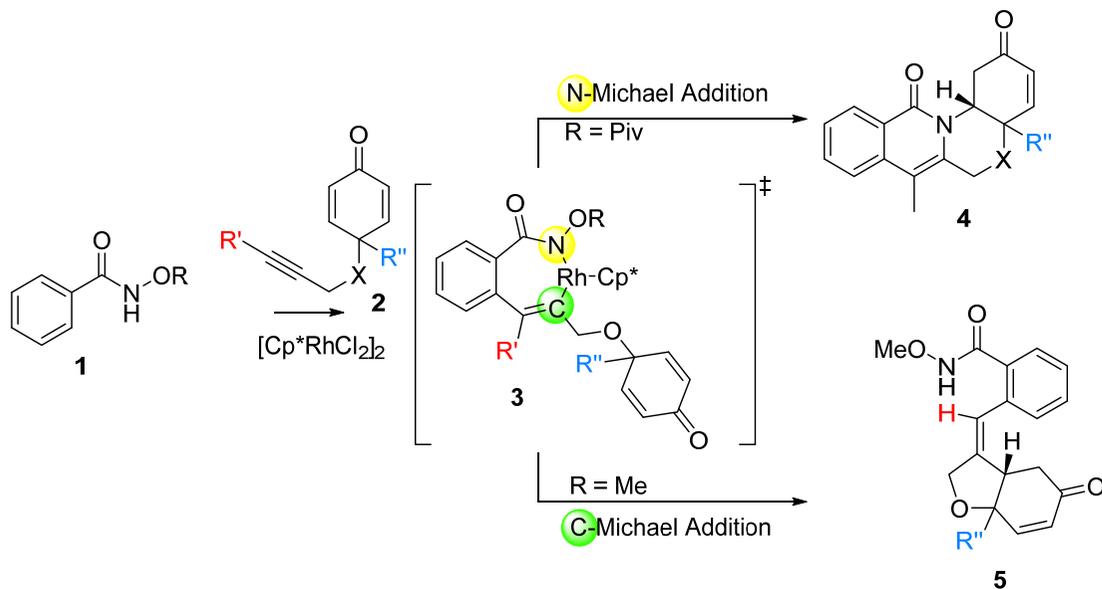
					New class of amino acid derived ligands	
40		Arylation	Ar-Bpin		Substrate (0.1 mmol), ArBpin (0.3 mmol), Pd(OAc) ₂ (10 mol%), Ac-Gly-OH (20 mol%), Ag ₂ CO ₃ (0.2 mmol), TBAPF ₆ (0.3 mmol), CsF (0.2 mmol), HFIP (1 mL), 70 °C, 24 h 24 Examples; Yield: 44-85% R ¹ = Halogen, CF ₃ , Me, OMe R ² = F, Me, OMe, CF ₃	234
41		Alkoxylation	R ² OH		Substrate (1 equiv), PhI(OAc) ₂ (1 equiv), Pd(OAc) ₂ (10 mol%), R ² OH, 25 °C 15 Examples; 47-95% Methanol, ethanol and <i>i</i> -propanol investigated R ¹ = Halogen, Me, OMe, NO ₂ , CF ₃ , Ph	174
42		Alkylation			Substrate (0.1 mmol), hypervalent alkynyl iodine reagent (0.11 mmol), NaOAc (0.1 mmol), [Cp* <i>RhCl</i>] ₂ (0.002 mmol), DCE (0.5 mL), 16 h, rt 18 Examples; Yield: 25-87% R ¹ = Aryl, Bn, alkyl R ² = Alkyl, Ph	269
43		Alkynylation			Substrate (0.1 mmol), hypervalent alkynyl iodine reagent (0.11 mmol), NaOAc (0.1 mmol), [Cp* <i>RhCl</i>] ₂ (0.002 mmol), DCE (0.5 mL), 16 h, rt R can be aromatic or aliphatic, yields generally above 50% R ¹ = Aryl, alkyl R ² = Aryl, alkyl	270

44		Arylation	ArI		<p>Substrate (1 equiv), iodobenzene (2 equiv), AgOAc (2 equiv), Pd(OAc)₂ (10 mol%), acetic acid, 120 °C, sealed tube</p> <p>23 Examples; Yield: 8-84%</p> <p>R¹ = Me, OMe, halogen, NO₂, CF₃, Ph</p> <p>R² = Me, NO₂, halogen, OMe, CF₃</p> <p>Long reaction times (20-720 h)</p>	271
45		Halogenation	NXS		<p>Substrate (1 equiv), NXS (1.2 equiv), TFA (10 equiv), Pd(OAc)₂ (10 mol%), MeOH, 25 °C</p> <p>Iodination, chlorination and bromination possible</p> <p>14 Examples; Yield: generally above 50%</p> <p>R = Halogen, Me, CF₃, NO₂</p> <p>Alkoxylation as common side reaction</p>	174

N-Methoxy amides as directing group

N-Methoxy amides are amongst the most widely used classes in amide based directing groups. A representative of particular interest is the Weinreb amide as it is an inherently valuable functional group. Wang et al. (Table 10, Entry 16)²⁷² presented a protocol for the direct *ortho* functionalization of aromatic Weinreb amides via Rh-catalysis. They were able to perform high yielding alkenylations in the presence of diverse functional groups including bromine in *meta* or *para*-position. This potentially allows for the orthogonal functionalization of different positions on the aromatic ring.

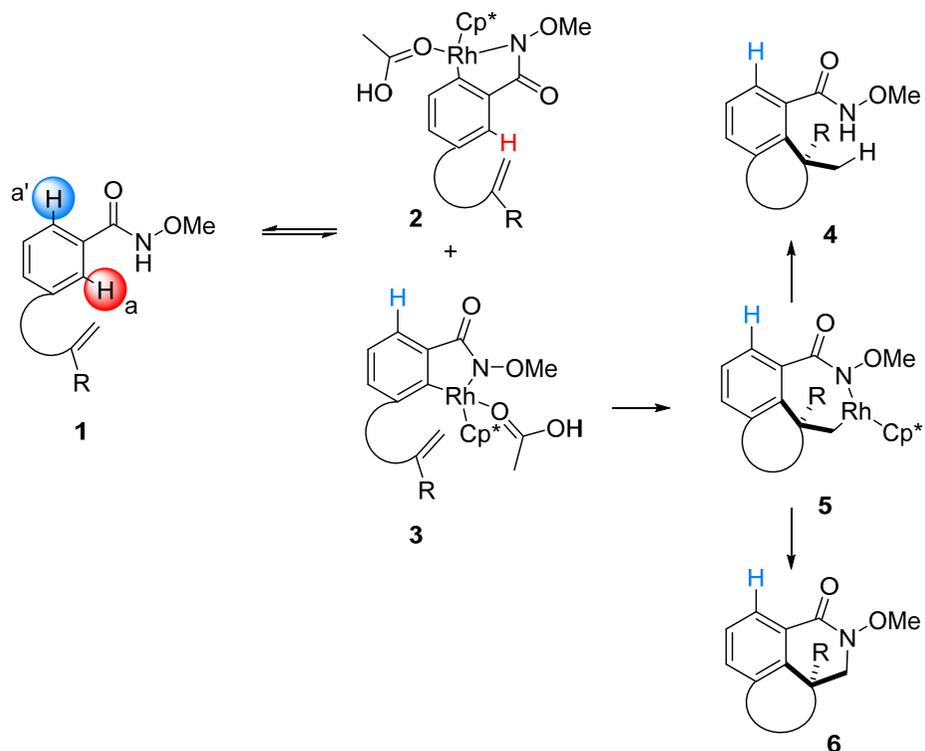
Li and coworkers²⁷³ presented a protocol for the aryative cyclization of 1,6-enynes towards either tetracyclic isoquinolones or hydrobenzofurans depending on the nature of the directing group used (Table 10, Entry 7 & 13). *N*-(Pivaloyloxy)benzamides might be involved in chelating the Rh(III)-intermediate via the *O*-pivaloyl group thereby promoting C-N bond reductive elimination, in the case of *N*-methoxybenzamides, an additional chelating is not possible resulting in the rapid protonation of the seven-membered rhodacycle and subsequently the formation of the open vinyl-Rh(III) intermediate.



Scheme 7: Formation of isoquinolines or hydrobenzofurans depending on the used directing group.

The *N*-methoxybenzamide motif was also used in the intramolecular transformation towards dihydrobenzofurans (Table 10, Entry 8).²⁷⁴ Starting from substrates of type 1, two possible positions for C-H insertion can lead to either functionalization at the less hindered α' position or, less likely, at the sterically more demanding α -position. Taking advantage of the reversibility of the insertion-process, the overall equilibrium is driven towards the seven membered rhodacycle 3. From here, reductive C(sp³)-N bond

formation or proto-demetalation yielding the desired **4** can occur. In the case of the C(O)-NHOMe directing group²⁷⁵, the β -elimination towards **5** is usually observed with Rh-catalysis which could be successfully suppressed via addition of PivOH (1 equiv) as additive and good to excellent enantiomeric ratios were reached.



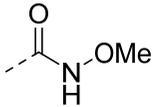
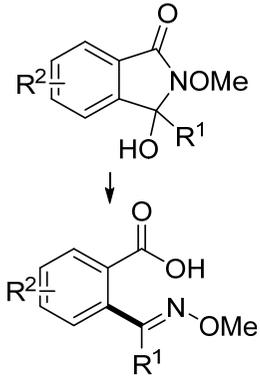
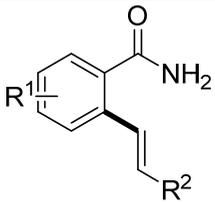
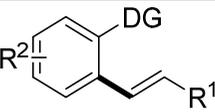
Scheme 8: Mechanistic rationale for the formation of the cyclized product 6.

The activation of C(sp³) carbon centers is usually a challenging task due to the inherently low activity of these centers. Yu and coworkers²⁷⁶ investigated the stereoselective β -arylation of modified alanine (Table 10, Entry 10). Via a 2-step Pd-catalyzed protocol with extremely broad substrate scope, the β -position of the protected amino acid could be substituted with 2 different aryl groups. The process could be realized in synthetically useful yields over 2 steps with good diastereomeric ratios.

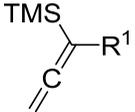
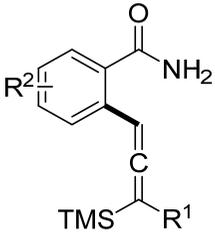
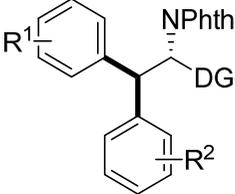
Geminal disubstituted allenylsilanes have been submitted to Ru-catalyzed aromatic C-H allenylation by Nakanowatari et al. (Table 10, Entry 9)²⁷⁷. Allenes are enormously versatile functional groups for further modification, their use in C-H activation is however fairly rare. Employing a Ru-catalyst and substituted *N*-methoxybenzamides, terminal allenylsilanes with various substituents could be connected to the *ortho* position of the aromatic substrates.

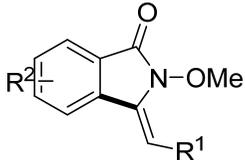
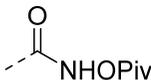
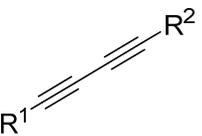
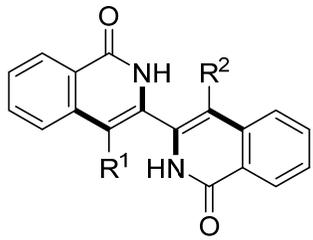
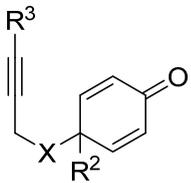
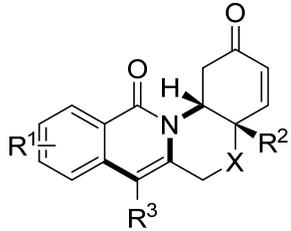
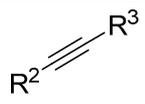
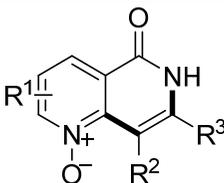
The utilization of diynes as coupling partners in alkenylation followed by intramolecular cyclization gives rise to the synthesis of unsymmetrical heterocyclic products. The Glorius group realized the coupling of diynes including unsymmetrical substrates and could thereby show the preparation of a number of bisheterocyclic compounds (Table 10, Entry 12).²⁷⁸

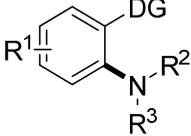
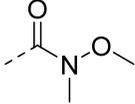
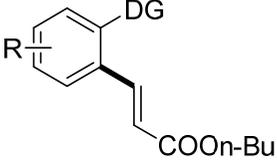
Table 10: N-Methoxy amides as directing group

Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
1		Acylation			Substrate (0.3 mmol), aldehyde (1.2 mmol), Pd(OAc) ₂ (10 mol%), TBHP (70% / H ₂ O; 5 equiv), BF ₃ ·Et ₂ O, (0.4 equiv), DMSO/dioxane (4/1; 0.2 M), 130 °C, 1.5-3 h 13 Examples; Yield: 51-72% R ¹ = Aryl R ² = Halogen, OMe, Me	²⁷⁹
2		Alkenylation			Substrate (1 equiv), [Cp*RhCl ₂] ₂ (1 mol%), CsOAc (30 mol%), MeOH (0.2 M), 60 °C, 3-16 h 35 Examples; Yield: 40-99% R ¹ = NO ₂ , Ac, COOMe, halogen, Ph, OMe; thiophene tolerated R ² = Aryl, heteroaryl, COOR <i>N</i> -Methoxy group cleaved during reaction	²⁸⁰
3		Alkenylation			Substrate (1 equiv), alkene (1.8 equiv), [RuCl ₂ (<i>p</i> -cymene)] ₂ (5 mol%), NaOAc (30 mol%), MeOH (0.2 M), 60 °C, 4-24 h 19 Examples; Yield: 45-95% R ¹ = COOR R ² = Alkyl, OMe, halogen, NO ₂ , CF ₃ , OAc, COOMe; thiophene and indole tolerated	²⁸¹

4		Alkenylation / Cyclization			Substrate (0.3 mmol), alkyne (0.9 mmol), 5% Pd/C (10 mol%), NaI·2H ₂ O (0.15 mmol), Na ₂ CO ₃ (0.3 mmol), DMF (1 mL), 48 h, air 17 Examples; Yield: 22-92% R ¹ = Alkyl, aryl, F R ² = Alkyl, aryl, F; in most cases R ¹ =R ² R ³ = Alkyl, OMe, Cl	282
5		Alkenylation and Intramolecular Cyclization			Substrate (1 equiv), alkene (2 equiv), [RuCl ₂ (<i>p</i> -cymene)] ₂ (10 mol%), NaOAc (200 mol%), CF ₃ CH ₂ OH (0.25 M), 50 °C, 24-36 h 10 Examples; Yield: generally above 50% R = Me, OMe	281
6		Alkoxylation	Alcohol		Substrate (0.25 mmol), Pd(OAc) ₂ (0.0125 mmol), K ₂ S ₂ O ₈ (0.5 mmol), 4 Å MS (30 mg), alcohol (2 mL), dioxane (2 mL), 55 °C 21 Examples, 20-79% yield R ¹ = Me, Halogen, NO ₂ , COOR R ² = Alkyl	283
7		Alkynylation/Arylative Cyclization			Substrate (0.3 mmol), 1,6 enyne (0.2 mmol), [Cp*RhCl ₂] ₂ (0.005 mmol), CsOPiv (2 equiv), PivOH (2 equiv), DCE (2 mL), 60 °C, 12 h 20 Examples; Yield: generally above 50% R ¹ = F, Br, OMe, CF ₃ , NO ₂ , COOMe, Me R ² = Alkyl,	273
8		Intramolecular Alkylation			Substrate (0.1 mmol), PivOH (0.1 mmol), chiral Rh-catalyst (5 μmol), (Bz) ₂ O (5 μmol), DCM (0.2 M), 23 °C, 12 h 15 Examples; Yield: above 50%, e.r. >92:8	274, 284

					$R^1 = \text{OR}, \text{OH}, \text{Ph}$ $R^2 = \text{OMe}, \text{OH}, \text{NO}_2, \text{Alkyl}, \text{Br}$ $X = \text{O}, \text{NMe}$	
9		Allenylation			Substrate (0.5 mmol), Allene (0.53 mmol), $[\text{RuCl}_2(p\text{-cymene})]_2$ (5 mol%), NaOAc (30 mol%), MeOH 83 mL), 22 °C, 18 h, N_2 22 Examples; Yield: 12-75% <i>N</i> -OMe cleaved during reaction $R^1 = \text{Alkyl}$ $R^2 = \text{Me}, \text{OMe}, \text{Halogen}, \text{CF}_3, \text{Ph}$	277
10		Arylation	ArI		Sequential process – R^1 Substrate (0.1 mmol), ArI (0.15 mmol), $\text{Pd}(\text{OAc})_2$ (10 mol%), AgOAc (0.2 mmol), 2-picoline (20 mol%), HFIP (1 mL), 75 °C, 24 h 46 Examples, 42-94% $R^1 = \text{Halogen}, \text{Me}, \text{OMe}, \text{Ph}, \text{C}(\text{O})\text{Me}, \text{COOR}, \text{NHAc}, \text{PO}(\text{OEt})_2, \text{CH}_2\text{OH}$ Heteroarene iodide susceptible to reaction conditions - R^2 Substituted substrate (0.1 mmol), ArI (0.3 mmol), $\text{Pd}(\text{OAc})_2$ (10 mol%), AgOAc (0.2 mmol), 2,6-lutidine (20 mol%), $\text{NaHPO}_4 \cdot \text{H}_2\text{O}$ (0.3 mmol), HFIP (1 mL), 100 °C, 36 h 12 Examples, > 50% yield $R^2 = \text{Me}, \text{CF}_3, \text{COOR}$	276

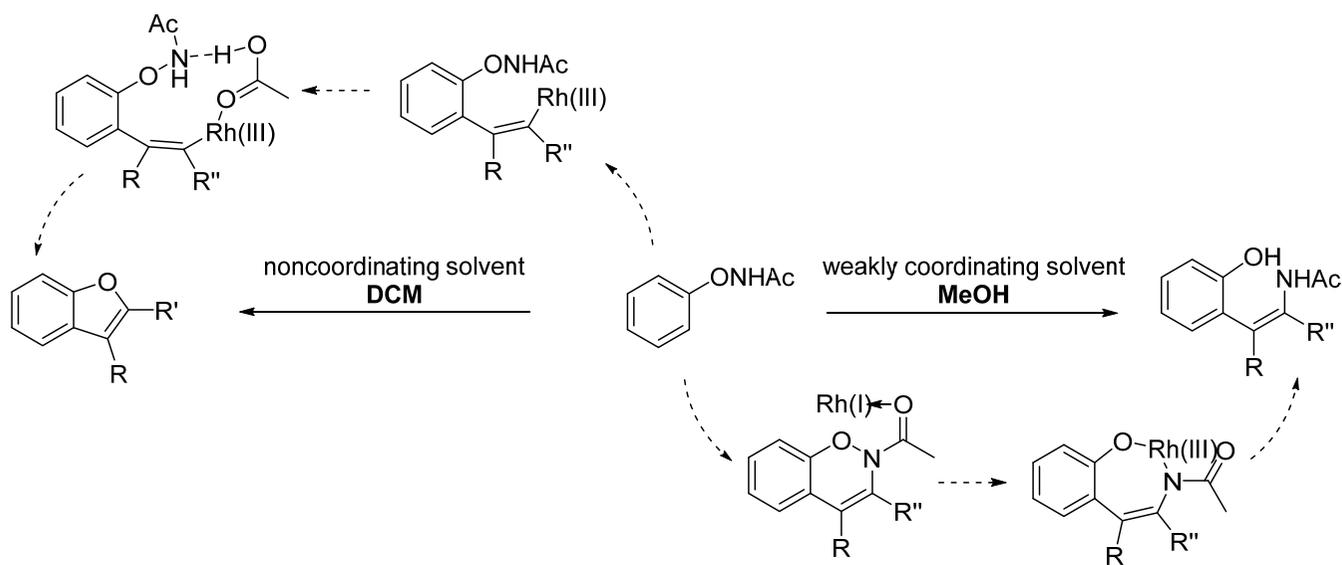
11		Isocyanade Insertion	R^1 -NC		Substrate (0.5 mmol), isocyanide (0.75 mmol), Pd(OAc) ₂ (0.05 mmol), O ₂ (balloon), Cs ₂ CO ₃ (0.75 mmol), toluene, 90 °C, 16 h 17 Examples, 45-91% yield R ¹ = ^t Bu, ⁱ Pr R ² = Halogen, Me, OMe, COOMe	285
12		Dual Alkenylation / Cyclization			Substrate (0.6 mmol), diyne (0.25 mmol), [Cp* ₂ Ir] (2 mol%), NaOAc (0.6 equiv), MeOH, 40 °C, air, 9 h 6 Examples, 67-80% yield R ¹ = Alkyl, aryl, TMS R ² = Alkyl, aryl, TMS Procedure applicable for the synthesis of unsymmetrical compounds	278
13		Alkynylation/Ary lative Cyclization			Substrate (1.5 equiv), 1,6 enyne (0.2 mmol), [Cp* ₂ RhCl ₂] (0.005 mmol), CsOAc (2 equiv), acetone (1 mL), 50 °C 20 Examples; Yield: generally above 50% R ¹ = Me, CF ₃ , OMe, F, Br R ² = Alkyl R ³ = Alkyl	273
14		Alkynylation / Intramolecular Cyclization			Substrate (1 equiv), alkyne (1.1 equiv), NaOAc (0.5 equiv), [Cp* ₂ RhCl ₂] (1 mol%), MeOH, 20 °C 16 examples, 1 example below 50% R ¹ = Br, OH, OMEM, CF ₃ , NHAc, COOMe R ² = H, Alkyl R ³ = Alkyl	275

15		Amination	<i>N</i> -Chloroamine		<p>Substrate (1 mmol), <i>N</i>-chloroamine (2 mmol), [Cp*RhCl₂]₂ (0.05 mmol), CsOAc (2 mmol), PivOH (0.5 mmol), MeOH (5 mL), 16 h, rt</p> <p>19 examples, only secondary, mostly cyclic amines investigated, yields between 30 and 85%</p> <p>R¹ = Alkyl, Ph, COOMe, OMe, halogen, CF₃</p> <p>R₂ – R₃ = Alkyl</p>	286
16		Alkenylation			<p>Weinreb amide (0.2 mmol), alkene (0.3 mmol), [Cp*RhCl₂]₂ (1 mol%), AgSbF₆ (4 mol%), Cu(OAc)₂ (20 mol%), DCE (0.7 mL), 120 °C, 16 h</p> <p>18 Examples, 38-98% yield</p> <p>R = Halogen, Me, NO₂, CN, Ph, OAc, OMe</p>	272

N-Acyl- containing directing groups

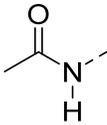
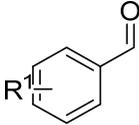
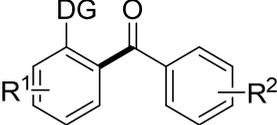
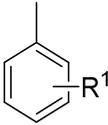
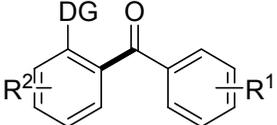
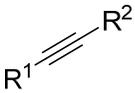
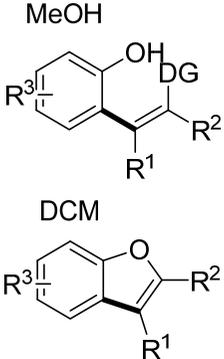
N-Acyl –substituents are commonly used as directing groups which is also due to the activating effect of this motif. A protocol for the mild *ortho* acylation of *N*-acetanilides was presented by Szabo et al. (Table 11, Entry 1)²⁸⁷ Aromatic as well as aliphatic aldehydes could be directly coupled to numerous *N*-acetanilides with good functional group tolerance due to the very mild conditions. The reaction could be conducted under air in aqueous media. Under more forcing conditions (100°C in DMSO), the same class of products could be prepared starting from toluene derivatives by Yin and Sun (Table 11, Entry 2).²⁸⁸ TBHP (4 equiv) serves as external oxidant producing the reactive acyl radical which adds to the palladacycle formed between Pd(II) and the acetanilide.

The tendency of *N*-*O* bonds to be cleaved during oxidizing coupling reactions was the rationale in the *ortho* alkenylation of *N*-phenoxyacetamides (Table 11, Entry 3).²⁸⁹ Via the choice of solvent the reaction outcome could be controlled either towards the formation of benzofuran-derivatives or *ortho*-hydroxyphenyl-substituted derivatives (Scheme 9). The transformation showed good selectivity and a broad substrate scope.



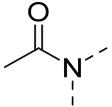
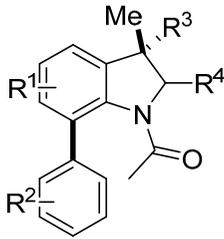
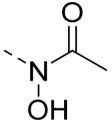
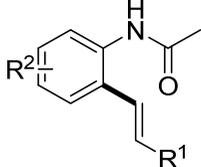
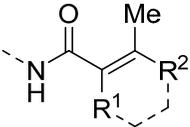
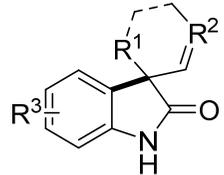
Scheme 9: Formation of benzofurane- or *ortho*-hydroxyphenyl- derivatives depending on the applied solvent.

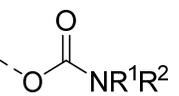
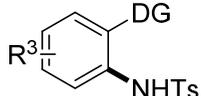
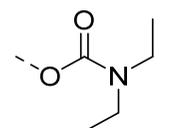
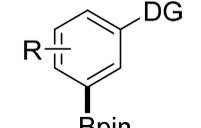
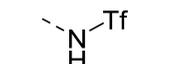
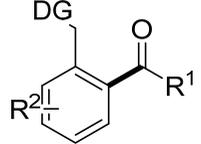
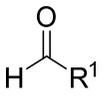
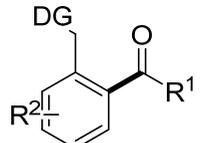
Table 11: *N*-Acyl- containing directing groups

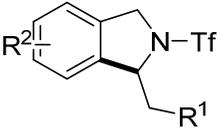
Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
1		Acylation			Substrate (1 mmol), benzaldehyde (2 mmol), Pd(OAc) ₂ (0.05 mmol), TFA (0.26 mmol), TBHP (2 mmol, 70 w% in water), rt, 24 h 20 examples, 32-86% yield R ¹ = Halogen, alkyl, OMe, R ² = Halogen, OMe - Aqueous conditions - Aliphatic aldehyde applicable	287
2		Acylation			Substrate (0.5 mmol), toluene derivative (1 mmol), Pd(OAc) ₂ (5 mol%), TBHP (2 mmol), DMSO (1 mL), 100 °C, air, 20 h 28 examples, 9-93% yield R ¹ = Halogen, Me, OMe R ² = Me, OMe, NO ₂ , halogen Formation of acyl-radical via benzylic oxidation	288
3		Alkenylation/Intramolecular Cyclization			Substrate (0.24 mmol), alkyne (0.2 mmol), [(Cp* <i>Rh</i> Cl ₂) ₂] (2.5 mol%), CsOAc (0.25 equiv), HOAc (1.2 equiv), MeOH (0.5 mL) or DCM (0.5 mL), 12-48h 29 examples in total, 45-90% yield R ¹ = Aryl, COOR, R ² = Ph, Alkyl R ³ = Me, CF ₃ , F - 2 mechanistic pathways proposed according to solvent	289

4		Alkenylation / Cyclization			Substrate (0.3 mmol), alkyne (0.63 mmol), Pd(OAc) ₂ (5 mol%), TsOH (0.15 mmol), K ₂ S ₂ O ₈ (0.6 mmol), toluene (1.5 mL), 16 h 12 Examples, 55-93% yield R ¹ = Aryl R ² = Me	290
5		Alkoxylation	ROH		Substrate (0.3 mmol), R ¹ OH (10-50 equiv), Pd(OAc) ₂ (0.03 mmol), K ₂ S ₂ O ₈ (0.6 mmol), MeSO ₃ H (0.06 mmol), DME (2 mL), rt, 24 h 22 Examples, 38-77% yield R ¹ = Alkyl R ² = Me, Cl, C(O)CH ₃	291
6		Arylation	ArB(OH) ₂		Substrate (1 equiv), ArB(OH) ₂ (2 equiv), Pd(OAc) ₂ (10 mol%), Cu(OTf) ₂ (2 equiv), K ₂ CO ₃ (2 equiv), dioxane, 80 °C, 16 h 19 Examples, 57-90% yield R ¹ = OMe, Me, halogen R ² = Me, Cl, NO ₂ , OMe X = CH ₂ , O	292, 293
7		Trifluoromethylat ion			Substrate (0.1 mmol), Umemoto's reagent (0.15 mmol), Pd(OAc) ₂ (10 mol%), Cu(OAc) ₂ (0.22 mmol), PivOH (0.5 mmol), DCE (1 mL), N ₂ , 110 °C, 24 h 19 examples, 41-83% yield R = Alkyl, halogen, COOR, C(O)R, OAc, Ph <i>m</i> -OMe and <i>m</i> -CF ₃ not tolerated	294

8		Acetoxylation	AcOH		Substrate (1 mmol), Pd(OAc) ₂ (0.05 mmol), K ₂ S ₂ O ₈ (2 mmol), AcOH (5 mL), DCE (5 mL), 100 °C, 48 h 13 Examples, 22-93% yield R ¹ = Me, OMe, halogen, C(O)CH ₃	295
9		Alkenylation			Substrate (3 mmol), <i>n</i> -butyl acrylate (3.3 mmol), Pd(OAc) ₂ (0.06 mmol), BQ (3 mmol), AcOH/toluene, TsOH (1.5 mmol), 20 °C 9 Examples, 30-91% yield R = Me, OMe, CF ₃	296
10		Arylation	ArB(OH) ₂		Substrate (0.2 mmol), boronic acid (0.4 mmol), Pd(OAc) ₂ (5 mol%), Cu(OTf) ₂ (1 equiv), Ag ₂ O (1 equiv), toluene (4 mL), 120 °C 24 Examples, 20-92% yield R ¹ = Me, OMe, Ph, F, NO ₂ R ² = Me, -(CH ₂) ₅ -, -(CH ₂) ₆ -	297
11		Oxidative Alkenylation			Substrate (0.54 mmol), acrylate (1.08 mmol), [RhCp*Cl ₂] ₂ (0.0216 mmol), Ag ₂ CO ₃ (1.08 mmol), CH ₃ CN (3 mL), 115 °C, 16 h, N ₂ 16 Examples, 33-89% yield R ¹ = Alkyl R ² = COOR, aryl R ³ = OMe, Br If R ² is an EWG, cyclization occurs	298
12		Arylation	ArI		Substrate (0.2 mmol), iodoarene (1.1 equiv), AgOAc (1.5 equiv), K ₃ PO ₄ (3 equiv), TFA (0.1 mmol), DCE (2 mL), 90 °C 20 Examples; Protocol for one-pot C-H activation and Suzuki	299

					coupling, 65-97% yield R ¹ = OMe, Me, Cl	
13		Arylation	Arene		Substrate (1 equiv), arene (solvent, 0.2 M), Pd(OAc) ₂ (20 mol%), Na ₂ S ₂ O ₈ (3 equiv), TFA (5 equiv), 100 °C or 120 °C 21 examples, yields generally above 50 % R ₁ = Me, OMe, F R ₂ = Me, Ph, OMe, OEt R ₃ = R ₄ = -(CH ₂) ₄ - R ₃ = Me, R ₄ = Me, - Dehydrogenerative C-H/C-H crosscoupling - Substituent at C2 (R ⁴) required	300
14		Alkenylation			Substrate (0.237 mmol), alkene (1.2 equiv), [RhCp*Cl ₂] ₂ (3 mol%), AgSbF ₆ (12 mol%), NaOAc (2 equiv), dioxane (2 mL), 100 °C, 8 h 19 Examples, 48-81% yield R ¹ = COOR, aryl R ² = Me, OMe, halogen, CN, COOR, CHO, C(O)Me, OH - N-OH is removed during reaction	301
15		Intramolecular Cyclization			Substrate (1 equiv), Pd(OAc) ₂ (2 mol%), methyl nicotinate (8 mol%), mesitylene/ <i>t</i> BuCOOH (4/1, 0.1 M), O ₂ , 24-230 h 12 Examples, 24-68% yield R ¹ = Me, Ph R ² = Me R ³ = OMe, Me, NMe ₂	302

16		Amidation	tosyl azide		<p>Substrate (0.36 mmol), tosyl azide (0.2 mmol), [IrCp*Cl₂]₂ (4 mol%), AgNTf₂ (16 mol%), Cu(OAc)₂ (10 mol%), DCE (0.5 mL), 50 °C, 12 h</p> <p>8 Examples, R₁ and R₂ = Me or Et, yields above 50%</p> <p>R₃ = Me, OMe, CF₃, NO₂, halogen, COOMe, CH₂OR,</p>	241
17		Borylation	B ₂ pin ₂		<p>Substrate (1 equiv), [Ir(cod)(OMe)]₂ (2 mol%), dtbpy (4 mol%), B₂pin₂ (0.6 equiv), hexanes, 80 °C, 18 h</p> <p>8 Examples, 16-82% yield</p> <p>R = TMS, halogen, OMe,</p> <ul style="list-style-type: none"> - Substitution in meta position - If a <i>o</i>-TMS is present, substitution occurs in para position 	230
18		Acylation	R ¹ CH ₂ OH		<p>Substrate (0.3 mmol), Alcohol (1.8 mmol), Pd(OAc)₂ (10 mol%), TBHP (1.2 mmol), AcOH (50 mol%), MeCN (1 mL), 120 °C, 40 h</p> <p>18 Examples, 30-84% yield</p> <p>R¹ = Aryl, Alkyl</p> <p>R² = OMe, Halogen</p> <ul style="list-style-type: none"> - The alcohol reaction partner is oxidized by TBHP to the corresponding acyl radical 	303
19		Acylation			<p>Substrate (0.3 mmol), aldehyde (0.9 mmol), Pd(OAc)₂ (5 mol%), TBHP (3 equiv), AcOH (50 mol%), MeCN/DMF (1/1, 0.6 mL), 100 °C, 20 h</p> <p>24 Examples, 13-75% yield</p> <p>R¹ = Aryl, Alkyl</p> <p>R² = OMe, Me, COOMe, Halogen</p>	304

20		Alkenylation/ Cyclization			<p><i>N</i>-Benzyltriflamide (0.3 mmol), Alkene (0.45 mmol), [RhCp*Cl₂]₂ (2.5 mol%), Cu(OAc)₂·H₂O (200 mol%), DMF- AcOH (3/1, 1 mL), 110 °C, 24 h, sealed tube 25 Examples, 21-93% R¹ = COOR, CN, C(O)R, CONMe₂ R² = Me, OMe, halogen, COOR</p>	305
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Directing groups containing the carbonyl motif

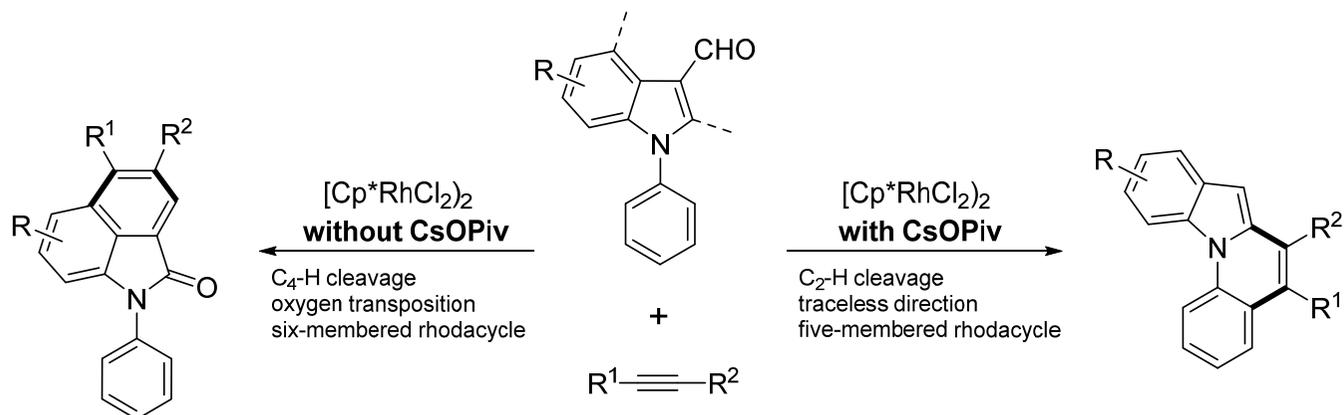
Carbonyl compounds such as esters, ketones and carboxylic acids are essential building blocks for the synthesis of fine chemicals, pharmaceuticals and natural compounds. From a synthetic point of view, weakly coordinating DGs such as carbonyl or electron rich functional groups (e.g. ethers, hydroxy) show several benefits due to low toxicity, ability for further transformations as well as that they can serve as traceless DGs (e.g. decarboxylation).³⁰⁶

Aldehydes as directing groups in C-H activation

Even though aldehydes are common functional groups in many organic compounds, they have been used as directing groups in only few examples (e.g. alkenylation,^{307, 308} annulation,^{309, 310} Table 12). The two main reasons are, the low directing ability (Table 12, Entry 4)³¹⁰ of aldehydes and additionally, their relatively high tendency to undergo side reactions. Besides classical imine- directed C-H functionalization, the *in situ* transformation of the aldehyde to the corresponding hydrazone allows an annulation reaction with alkynes at the *ortho* C-H bond of benzaldehyde derivatives. First, the aldehyde is transformed with NH₂NHAc to the corresponding hydrazone and after a reductive elimination, indenones were isolated in good yields after acidic hydrolysis. Finally, the catalyst is regenerated by oxidation of Ag(I) (Table 12, Entry 3).³⁰⁹

A highly regioselective alkenylation of indoles with high excess of Cu(OAc)₂·H₂O (50 mol%) for reactivation of the ruthenium catalyst under mild reaction conditions (open flask) has been shown as a straightforward strategy to synthesize 4-substituted indoles (Table 12, Entry 1).³ This compound class can serve as building blocks for alkaloids and related heterocyclic compounds.³⁰⁸

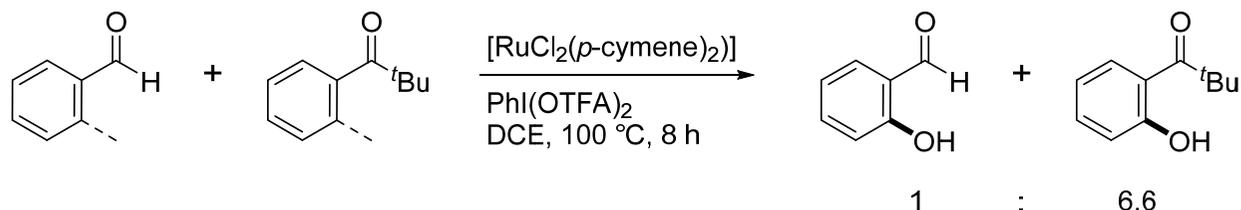
As mentioned in the case of carboxylate- directed C-H activation, the concept of traceless DGs (e.g. decarboxylation) (Table 14, Entry 16)³¹¹ is of great interest especially for a selective and atom efficient synthesis of fine chemicals or natural compounds. A novel rhodium-catalyzed regioselective C-H activation/cyclization of indolyl aldehydes or ketones with alkynes to the corresponding oxindoles in a cascade fashion was reported (Table 12, Entry 4).³¹⁰ During optimization studies, tetrahydrofuran and a catalyst loading of 3.5 mol% resulted in improved yields, but interestingly the choice of the oxidant (Ag₂CO₃) and AgSbF₆ as an additive are crucial for the reaction. The mechanism involves several steps, first a Rh catalyzed C4-H activation followed by a [4+2] cyclization/aromatization and finally a nucleophilic addition of water leads the final motif (Scheme 10, left).



Scheme 10: Regioselective Rh- catalyzed cyclization depending on the presence of CsOPiv.

In 2015 the group of You showed the effect of CsOPiv to differentiate between C4-H (Scheme 10, left) and C2-H activation (Scheme 10, right) for similar starting materials. The rhodium catalysed C2-H activation/cyclization requires elevated temperature (140 °C), Cu(OAc)₂ as an oxidant in dioxane. This is another example for a traceless aldehyde DG and this procedure leads to bioactive indolo-[1,2-*a*]-quinolone derivatives (Table 12, Entry 5).³¹² In the published mechanism, they have stated that coordination of the carbonyl oxygen atom to Rh(III) and pivalate is required for C2-H bond activation to form a five-membered rhodacycle. After the insertion of the alkyne, protonolysis and recyclorhodation to a seven membered rhodacycle was proposed and this intermediate affords after reductive elimination the final product by regeneration of the Rh(III) catalyst.

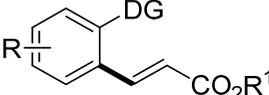
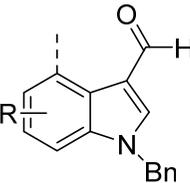
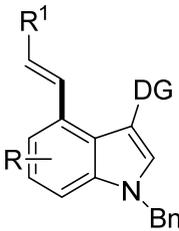
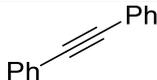
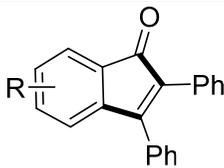
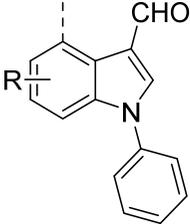
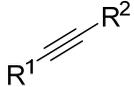
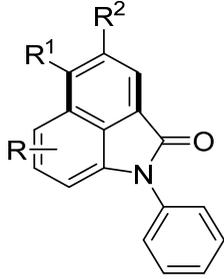
In 2014, the group of Ackermann reported the first aldehyde directed oxygenation catalysed *via* a ruthenium(II) complex for *ortho/ meta* and *para* substituted benzaldehyde derivatives with increased reactivity towards electron rich arenes. The optimized protocol consists of a rate-determining C-H metalation and the hypervalent iodine (III) reagent (PhI(OTFA)₂) is required as an oxidant but without further additives.

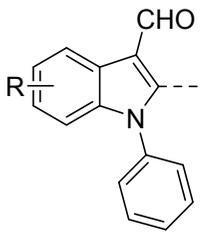
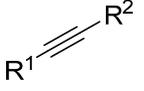
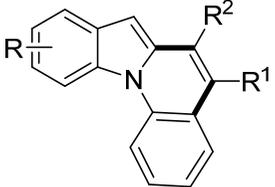
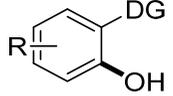


Scheme 11: Lack of directing power of aldehydes in C-H activation.

Intermolecular competition experiments between aldehyde to ketone (1: 6.6) or amide (1:17.5) directed oxygenation (Scheme 11), clearly show the bottleneck of the weakly coordinating aldehydes due to significantly lower directing activity and product formation (Table 12, Entry 6).³¹³

Table 12: Aldehydes as directing groups in C-H activation reactions

Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
1		Alkenylation			Substrate (1 mmol), alkene (5- 6 mmol), [RuCl ₂ (<i>p</i> -cymene)] ₂ (3 mol%); AgSbF ₆ (20 mol%); Cu(OAc) ₂ ·H ₂ O (50 mol%), DCE, 100 °C, 16h, under air. 17 Examples; Yield: 25- 79% R= OMe, Me, NMe ₂ , Cl R ¹ = Alkyl, OH	³⁰⁷
2		Alkenylation			Substrate (1 equiv.), acrylate (4 equiv.), [Ru(<i>p</i> -cymene)Cl ₂] ₂ (10 mol %), AbSbF ₆ (20 mol %), Cu(OAc) ₂ ·H ₂ O (1 equiv.), DCE, 120 °C, air. 15 Examples; Yield:50- 95% R= Alkyl, alkoxy, halogen R ¹ = COOMe, CHO	³⁰⁸
3		Annulation			Substrate (0.2 mmol), alkyne (0.3 mmol), [Cp*Rh(MeCN) ₃](SbF ₆) ₂ (5 mol%), AgSbF ₆ (20 mol%), Ag ₂ CO ₃ (1.0 equiv.), NH ₂ NHAc (1.1 equiv.), HOAc, 120 °C. 12 Examples; Yield: 48-80% R= Alkyl, alkoxy, halogen, CF ₃	³⁰⁹
4		Annulation, Oxygen transposition			Substrate (2 mmol), alkyne (0.25 mmol), [Cp*RhCl ₂] ₂ (3.5 mol%), AgSbF ₆ (14.0 mol%), Ag ₂ CO ₃ (1.2 equiv.), THF, 120 °C, 24h 38 Examples; Yield: 30-75% R= Me R ¹ & R ² = Substituted aryl (OMe, F, Cl, Br)	³¹⁰

5		Cyclization			Substrate (0.375 mmol), alkyne (0.25 mmol), [Cp*RhCl ₂] ₂ (5 mol%), Cu(OAc) ₂ (2.1 equiv.), CsOPiv (2.0 equiv.), dioxane, 140 °C, 24h, nitrogen. 24 Examples; Yield: 61-95% R= Me, OMe, OBn, COOMe, CN R ¹ & R ² = Ph, Me, halogen	312
6		Hydroxylation	PhI(OTFA) ₂		Substrate (0.5 mmol), [RuCl ₂ (<i>p</i> -cymene) ₂] (2.5 mol%), PhI(OTFA) ₂ (1.5-2.5 equiv.), DCE, 100 °C, 8h. 23 Examples, Yield: 41-72% R= Alkyl, alkyoxy, Ph, halogen	313

Carboxylic acid- based directing groups

In contrast to well-studied DG's such as pyridine, oxazoline, carboxylate-directed C-H activation shows some advantages: cleavage ability, easy to synthesise from other functional groups and availability in organic compounds and a variety of protocols (e.g. alkenylation,³¹⁴⁻³¹⁶ arylation,^{311, 317, 318} hydroxylation^{319, 320} etc.) are summarized in the following Table 13.

First published C-H activation on benzoic or naphthoic acids was performed by Miura *et al.* already in 1998 (Table 13, Entry 17).³²¹ In comparison to the well-studied ruthenium catalysed ketone (Table 15) or carboxylic acid ester (Table 14) directed alkylation reactions, carboxylate directed alkylation reactions (Table 13) promoted by Pd(OAc)₂ and Cu(OAc)₂ in DMF provided a new access to alkylation reactions. This procedure gave access to phthalides or isocoumarins *via* an *ortho*-vinylation/nucleophilic cyclization or Wacker type oxidative cyclization.

The group of Yu presented several alkenylation reaction (Table 13, Entry 1, 2, 4, 5)^{314-316, 322} promoted by Pd(OAc)₂ in ^tAmyl-OH combined with different amino acid ligands. The choice of amino acid ligand effects besides the conversion rate mainly the regioselectivity of the reaction, for example *ortho* or *meta* alkenylation reactions of phenoxyacetic acids (Table 13, Entry 1, 4).^{316, 322}

Another major goal for carboxylate-directed C-H functionalisation are one pot processes, containing traceless directing groups that do not require additional steps for DG cleavage. A carboxylate directed *ortho*-alkenylation of benzoic acids with styrene derivatives, catalysed by a rhodium catalyst combined with the cleavage ability of the carboxyl group *via* decarboxylation at 160 °C for 4 h was reported (Table 13, Entry 6)³²³ and for this case the arrows indicate the former position of the traceless DG. Another example, using a removable carboxylate directing group and a weakly coordinating auxiliaries is the *ortho*- & *meta* selective alkylation of phenol derivatives to synthesise biologically important α -phenoxyacetic acids (Table 13, Entry 4).³¹⁶ To control the regioselectivity of this Pd(II) promoted alkylation towards the *meta* position, the carboxylated directing scaffold is exchanged by an CN motif combined with an amino acid ligand system to perform *meta* selective olefination reactions in good yields.

Annulation reaction can be performed *via* Pd, Rh and Ru but nearly all of these procedures requires CuOAc₂·H₂O as oxidizing agent for cyclization. In general, benzoic acid derivatives serves as substrates, which undergoes annulation reactions with alkenes as well as alkynes. For the second mentioned type of reaction, the regioselectivity of the alkyne insertion is controlled by (Table 13, Entry 14)³²⁴

Alternatively, lactonization depicts a common cyclization methodology to synthesise different lactones starting for aromatic benzoic acid derivatives. This type of transformation is mainly catalyzed by Pd but also Cu and Rh complexes at high temperatures (80-150 °C) are represented. A novel Pt catalyzed lactonization

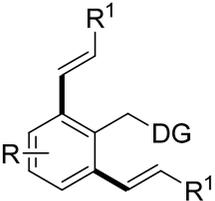
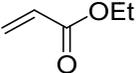
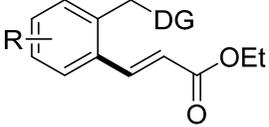
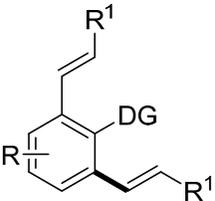
procedure in water was developed by the group of Chang (Table 13, Entry 33).³²⁵ This transformation starts with an unusual activation of a sp³ C-H bond and leads to seven and eight membered lactones at 150 °C in moderate to good yields (20-65%).

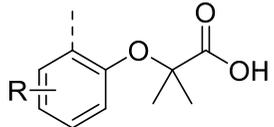
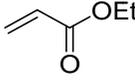
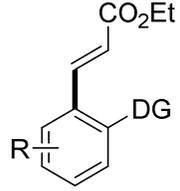
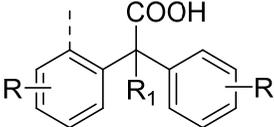
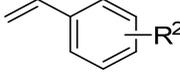
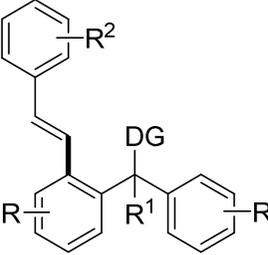
Also for carboxylic acids as directing group, arylation reactions have been developed using a number of different conditions and aryl sources, mainly aryl iodides and some specific example with ArBF₃K, ArB(OR)₂ have been used. As can be seen, Pd(OAc)₂ is the catalyst precursor of choice and typically no additional ligand was added. Typically high temperatures are required (100-130 °C) and only two examples reported good results already at 80 °C (Table 13, Entry 19 & 20).^{326, 327} In contrast to all given examples, the group of Su showed an arylation of benzoic acid with substituted aryl iodides at low temperature. Especially the solvent choice HFIP is responsible to decrease the reaction temperature to 30°C (Table 13, Entry 21).³²⁸ Dastbaravardeh *et al.* presented a very modular carboxylate directed C-H functionalization of mandelic acid and α -phenylglycine mediated by Pd(OAc)₂ for arylation, acetoxylation, iodination and olefination reactions (Table 13, Entry 20).³²⁷ The modularity towards the different transformations under identical conditions (AgOAc, KOAc, HFIP, 80 °C) only by adapting the coupling agent gave the desired products in good yields within 24h. A direct *ortho* arylation of benzoic acids as well as a α -arylation of aryl acetic acid derivatives promoted by Pd(OAc)₂ are examples for under-represented aryl chlorides or bromides as coupling partner for carboxylate directed C-H functionalizations (Table 13, Entry 17 & 23).^{318, 329}

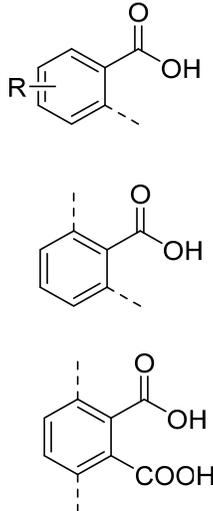
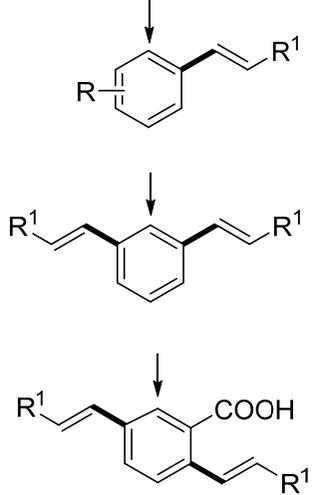
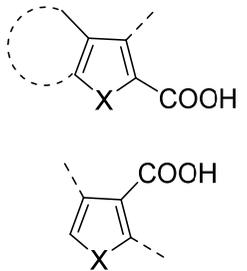
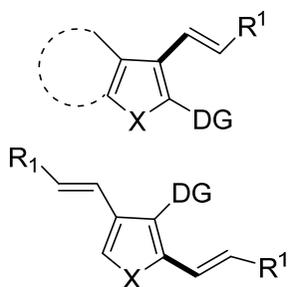
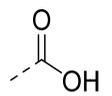
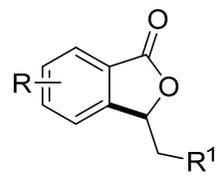
The group of Yu published a highly selective mono-carboxylation of benzoic acid and phenyl acetic acid derivatives and under optimized conditions. The optimized protocol was also applied to vinylic C-H bond (Table 13, Entry 24).³³⁰ A broad range of phthalic acids were synthesized *via* the generation of six-membered palladacycles³³⁰⁻³³² and the addition of inorganic cations (NaOAc) are crucial for stoichiometric carboxylation with 1 atm CO. Furthermore, the reactivation of Pd(0) to Pd(II) was limited to Ag₂CO₃ other oxidants like Ag₂O or Cu(OAc)₂ gave less than 10 % conversion.

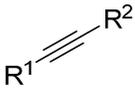
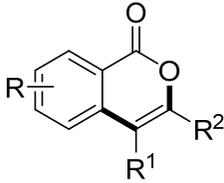
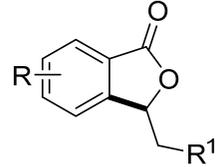
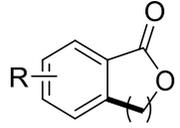
Besides a Cu(AcO)₂ catalyzed hydroxylation on the remote ring system (Table 13, Entry 25)³¹⁹ with limiting substrate consumption in the presence of oxygen, a highly selective Pd-catalyzed *ortho* oxygenations of potassium benzoates at 1 atm O₂ or air were published in 2009 (Table 13, Entry 26).³²⁰ Based on labelling studies with O¹⁸ or H₂¹⁸O the direct Pd(OAc)₂ mediated oxygenation was confirmed and the desired target molecules were obtained in good yields using the uncommon solvent (DMA) at 115°C. In contrast to electron rich arenes (yields up to 82 %), electron-withdrawing substituents gave decreased overall yields of around 50%.

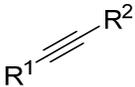
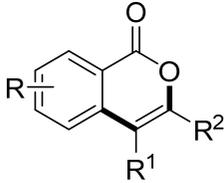
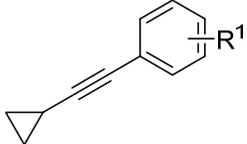
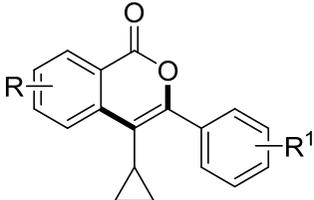
Table 13: Carboxylic acid- based directing groups

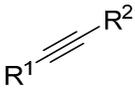
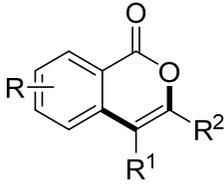
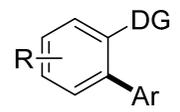
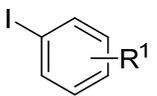
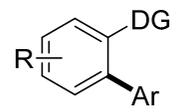
Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
1		Alkenylation			<p>Substrate (1. equiv.), acrylate (2 equiv.), Pd(OAc)₂ (5 mol%), Ac-Val-OH (10 mol%), KHCO₃ (2 equiv.), ^tAmyl-OH, 90 °C, 1 atm O₂, 6h.</p> <p>24 Examples; Yield: 35-91%</p> <p>R= Me, OMe, halogen, CF₃</p> <p>R¹= COOR (^tBu, Et, Bn)</p>	322
2		Alkenylation			<p>Substrate (1 equiv.), acrylate (2 equiv.), Pd(OAc)₂ (5 mol%), Ac-Ile-OH (10 mol%), KHCO₃ (2.0 equiv.), ^tAmyl-OH, 90 °C, 1 atm O₂, 48 h.</p> <p>11 Examples; Yield: 72-99%</p> <p>R= Me, OMe, halogen, NO₂, CF₃</p>	315
3		Alkenylation			<p>Substrate (0.5 mmol), alkene (1.5 mmol), [Cp*⁺RhCl₂]₂ (0.005 mmol), Ag(OAc) (2 mmol), DMF, 120 °C, 8-10 h, N₂ atm.</p> <p>14 Examples; Yield: 60-84 %</p>	333

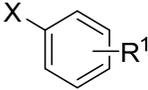
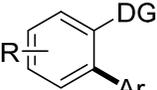
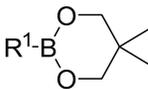
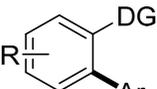
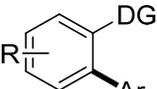
					R= Me, OMe, Ph, halogen, CF ₃ R ¹ = Aryl	
4		Alkenylation			Substrate (0.1 mmol), acrylate (0.2 mmol), Pd(OAc) ₂ (5 mol%), Boc-Val-OH (10 mol%), KHCO ₃ (0.2 mmol), ^t Amyl-OH, O ₂ , 90 °C, 24 h. 15 Examples; Yield: 58-88% R= Me, OMe, halogen, CF ₃	³¹⁶
5		Alkenylation			Substrate (0.5 mmol), Pd(OAc) ₂ (5 mol%), Boc-Ile-OH·0.5 H ₂ O (10 mol%), BQ (5 mol%), base (e.g. KHCO ₃) (0.5 equiv.), 1 atm O ₂ , ^t Amyl-OH, 90 °C, 48 h. 19 Examples; Yield: 39-73% R= Alkyl, OMe R ¹ = Alkyl R ² = Alkyl and halogen	³¹⁴

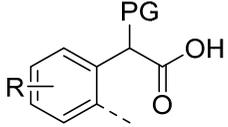
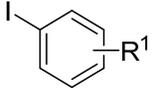
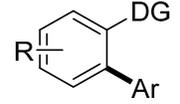
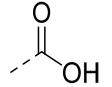
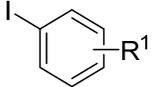
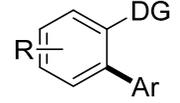
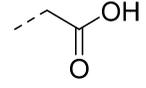
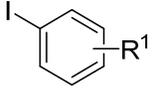
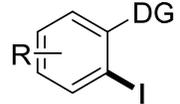
6		Alkenylation and Decarboxylation			<p>Substrate (0.5 mmol), alkene (1 mmol), [Cp*RhCl₂]₂ (0.005 mmol), AgOAc or Cu(OAc)₂ (1-1.5 mmol), DMF or DMAc, 100-120 °C, 10 h.</p> <p>9 Examples; Yield: 55-85%</p> <p>R = OMe, Ph, halogen</p> <p>R¹ = substituted Ph</p>	323
7		Alkenylation			<p>Substrate (0.25 mmol), acrylate (1.0 mmol), [Ru(p-cymene-Cl₂)₂] (0.005 mmol), Cu(OAc)₂·H₂O (0.5 mmol), LiOAc (0.75 mmol), DMF.</p> <p>13 Examples; Yield: 48-94%</p> <p>R¹ = COOR (alkyl), CONH(^tBu), CN</p> <p>X = S, O, NMe</p>	334
8		Alkylation/Cyclization			<p>Substrate (1 mmol), alkene (2.0 mmol), [RuCl₂(p-cymene)]₂ (2 mol%), Cu(OAc)₂·H₂O (2 mmol), H₂O; 80 °C.</p> <p>12 Examples; Yield: 51-95%</p>	335

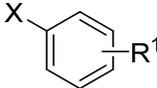
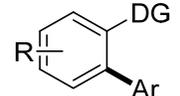
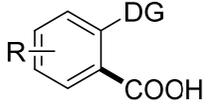
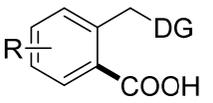
					R= Me, OMe, halogen R ¹ = COOR (R= alkyl), CN	
9		Annulation			Substrate (0.5 mmol), alkyne (0.6 mmol), [Cp*RhCl ₂] ₂ (0.005 mmol), Cu(OAc) ₂ ·H ₂ O (0.025 mmol), DMF, 120 °C, 2-10 h. 22 Examples; Yield: 42-99% R=Me, OMe, OH, CF ₃ R ¹ & R ² = Alkyl, Ph	336
10		Annulation			Substrate (1 mmol), acrylate (3 mmol), Pd(OAc) ₂ (0.1 mmol), Cu(OAc) ₂ ·H ₂ O (0.1 mmol), molecular sieve 4A (400 mg), DMF, 6-18 h. 5 Examples ; Yield: 34-59 % R= Me, OMe R ¹ = COOR (ⁿ Bu, Ph)	321
11		Annulation	Alkyl halide		Substrate (0.5 mmol) Pd(OAc) ₂ (5 or 10 mol%), base (e.g. K ₂ HPO ₄ or Na ₂ CO ₃ (3.0 equiv.)), 115-140 °C, 36 h.	337

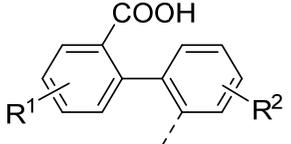
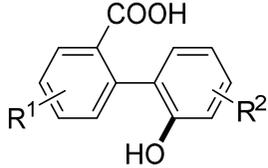
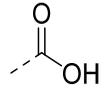
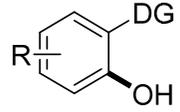
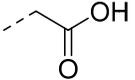
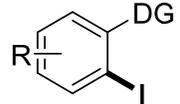
					<p>9 Examples; Yield: 26-81 %</p> <p>R= Me, OMe, CF₃, CPh</p> <p>Alkyl halide: ClCH₂CH₂Cl, CH₂Br₂, C₅H₁₁Cl</p>	
12		Annulation			<p>Substrate (0.5 mmol), alkyne (0.6 mmol), [Cp*RhCl₂]₂ (0.005 mmol), Cu(OAc)₂·H₂O (0.025 mmol), DMF, 120 °C, 2 h, under air.</p> <p>9 Examples; Yield: 83-97%</p> <p>R= Me, OMe, Cl</p> <p>R¹ & R²= Alkyl, Ph</p>	338
13		Annulation			<p>Substrate (4 equiv.), alkyne (2 equiv.), [RuCl₂(<i>p</i>-cymene)]₂ (2.5 mol%), KPF₆ (20 mol%), Cu(OAc)₂·H₂O, ^tAmyl-OH, 120 °C.</p> <p>6 Examples; Yield: 21-71%</p> <p>Regioselectivity 7/1</p> <p>R=Me, OMe</p> <p>R¹= Me, OMe, COOMe, CF₃</p>	339

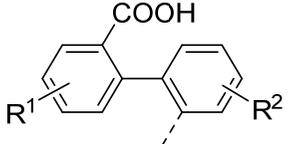
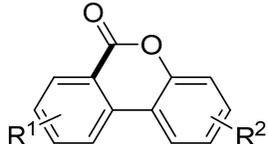
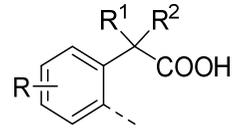
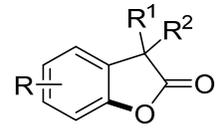
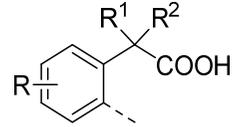
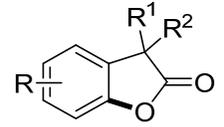
14		Annulation			<p>Substrate (2.0 mmol), alkyne (1 mmol), [RuCl₂(<i>p</i>-cymene)]₂ (2.5 mol%), KPF₆ (20 mol%), Cu(OAc)₂·H₂O, ^tAmyl-OH, 120 °C, 16 h.</p> <p>25 Examples; Yield: 60-87%</p> <p>R¹ & R²= Aryl, alkyl</p>	324
15		Arylation	Ar-BF ₃ K		<p>Substrate (1 eq), aryl trifluoroborate (1.2-1.5 equiv.), Pd(OAc)₂ (10 mol%), BQ (0.5 equiv.), K₂HPO₄ (1.5 equiv.), 20 atm O₂/air, ^tBuOH, 100 °C, 24 h.</p> <p>18 Examples; Yield: 41-91%</p> <p>R= Me, halogen, CF₃, CN, NMe₂</p>	317
16		Arylation			<p>Substrate (1 equiv.), aryl iodide (3 equiv.), Pd(OAc)₂ (2.0 mol%), Ag₂CO₃ (1.0 equiv.), AcOH (3.5 equiv.), 130 °C, 16h.</p> <p>18 Examples; Yield: 51-83%</p> <p>R= Halogen, OMe, NO₂, CF₃</p> <p>R¹= Me or halogen (mono or disubstituted)</p>	311

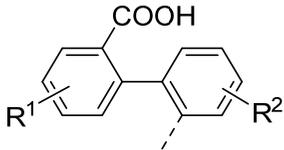
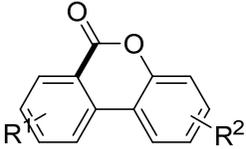
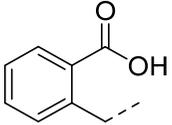
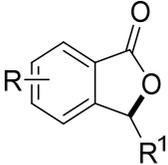
17		Arylation			<p>Substrate (1 mmol), aryl halide (1.5-3 eq), Pd(OAc)₂ (5.0 mol%), AgOAc (1.3 equiv.), AcOH (3.5 equiv.), 100-130 °C, 4.5-7 h.</p> <p>20 Examples; Yield: 53-91 %</p> <p>R= Me, OMe, halogen</p> <p>R¹= Alkyl, Cl, CF₃</p> <p>X= I, Cl</p>	318
18		Arylation			<p>Substrate (1 equiv.), benzoic acid (1-3 equiv.), Pd(OAc)₂ (10 mol%), Ag₂CO₃ (1 equiv.), BQ (0.5 equiv.), ^tBuOH, 100-120 °C, 3 h.</p> <p>6 Examples, Yield: 40-75%</p> <p>R=Me, OMe COOMe</p> <p>R¹ = Me, Ph</p> <p>Also for allyl acids</p>	340
19		Arylation	Ar-I		<p>Substrate (1 equiv.), aryl iodide (2 equiv.), Pd(OAc)₂ (5 mol%), AgTFA (1.3 equiv.), Tween 20/H₂O (2 % w/w), 80 °C.</p>	326

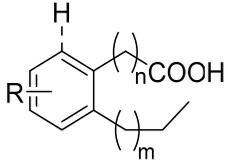
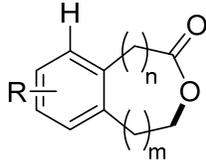
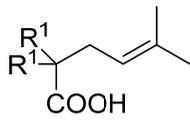
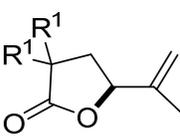
					15 Examples, Yield: 62-92% R= Me, F, CF ₃ , RCO	
20		Arylation			Substrate (0.1 mmol), aryl iodide (0.002 mmol), Pd(OAc) ₂ (0.01 mmol), AgOAc (0.2 mmol), KOAc (0.3 mmol), HFIP, 80 °C, 24 h, air. 15 Examples, Yield: 38-89% R=Cl, CF ₃ R ¹ = Me, OMe, COOMe, NO ₂ , CF ₃	327
21		Arylation			Substrate (0.2 mmol), aryl iodide (0.4 mmol), Pd(OAc) ₂ (8 mol%), Ag ₂ CO ₃ (0.5 equiv.), Cs ₂ CO ₃ (0.5 equiv.), HFIP, 30 °C. 35 Examples, Yield: 37-93% R= Me, halogen, CF ₃ , COOR, alkoxy R ¹ =Me, OMe, COOMe, Cl	328
22		Arylation			Substrate (1 equiv.), aryl halide (3 equiv.), Pd(OAc) ₂ (2 mol%), Ag ₂ CO ₃ (0.55 equiv.), K ₂ CO ₃ (0.5 equiv.), AcOH (4.5 equiv.), 120 °C, 24 h.	341

					23 18 Examples, Yield: 60-83 % R= Me, OMe, halogen R ¹ = Me, F, NO ₂ , CF ₃	
23		Arylation			Substrate (0.1 mmol), aryl halide (1 equiv.), Pd(OAc) ₂ (5 mol%), NiXantphos (7.5 mol%), (KNSiMe ₃) ₂ (3 equiv.), toluene, 110 °C, 12 h. 19 Examples, Yield: 49-82% R= Me, OMe, halogen R ¹ = Me, halogen X= Br, Cl	329
24		Carboxylation	CO	 	Substrate (1 equiv.), Pd(OAc) ₂ (10 mol%), Ag ₂ CO ₃ (2.0 equiv.), NaOAc (2.0 equiv.), 130 °C, 18 h, 1 atm CO, 1,4 dioxane. 26 Examples; Yield: 45-90% R= Me, Bn, OMe, halogen	330

25		Hydroxylation	LiOH		<p>Substrate (0.5 mmol), Cu(OAc)₂ (5.0 mol%), [PhCO₂]₂ (1.25 equiv.), HFIP (8 mL/ mmol), 75 °C, 12 h.</p> <p>Hydrolysis: LiOH, MeOH, r.t.</p> <p>25 Examples; Yield: 22-95 %</p> <p>R¹ & R² = Me, alkoxy</p>	319
26		Hydroxylation	O ₂		<p>Substrate (1 equiv.), Pd(OAc)₂ (10 mol%), KOAc (2.0 equiv.), BQ (1.0 equiv.), 1 atm O₂, DMA, 115 °C, 15 h.</p> <p>20 Examples; Yield: 35-82 %</p> <p>R = Me, OMe, halogen, CF₃, NO₂, CN, COMe</p>	320
27		Iodination	I ₂		<p>Substrate (1 mmol), Pd(OAc)₂ (2 mol%), PhI(OAc)₂ (0.75 equiv.), I₂ (0.75 equiv.), DMF, 60 °C, 12h, no light.</p> <p>23 Examples; Yield: 62-82%</p> <p>R = Alkyl, aryl, OPh, halogen, acetyl, CF₃</p>	342

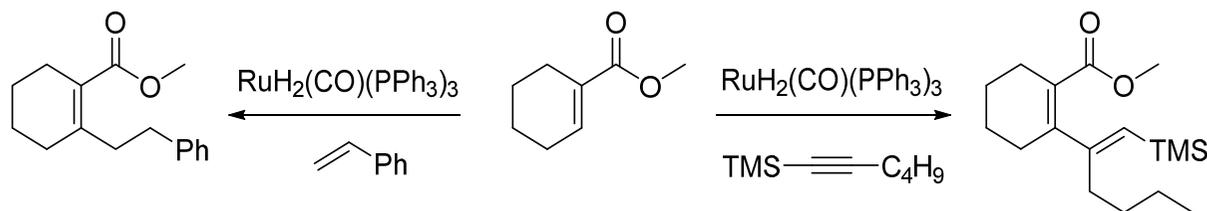
28		Lactonization			<p>Substrate (1 equiv.), Cu(OAc)₂·H₂O (5 mol%), PhCO₂OtBu (3 equiv.), DCE (0.1 M), 85 °C.</p> <p>30 Examples; Yield: 45-97%</p> <p>R¹ & R²= Alkyl, alkoxy</p> <p>substitution only on one aromatic ring, no example with R¹ and R² together</p>	343
29		Lactonization	-		<p>Substrate (0.2 mmol), Pd(OAc)₂ (10 mol%), PhI(OAc)₂ (2.0 equiv.), Ag₂OAc (0.5 equiv.), CsOAc/NaOAc (0.5/0.5 equiv.), PhCl/^tBuOH (1:1), 100 °C, 12 h.</p> <p>25 Examples; Yield: 35-89%</p> <p>R= Alkyl, alkoxy, aryl, halogen</p> <p>R¹ & R²=Me, cyclopropyl, cyclohexyl, Bn</p>	344
30		Lactonization	-		<p>Substrate (1 equiv.), Pd(OAc)₂ (5 mol%), Ac-Gly-OH (30 mol%), PhI(OAc)₂ (1.5 equiv.), KOAc (2.0 equiv.), ^tBuOH, 100 °C, 12 h.</p> <p>22 Examples; Yield: 50-90%</p>	345

					R= Alkyl, alkoxy, aryl, halogen R ¹ & R ² = Alkyl, cyclopropyl, cyclobutyl, cyclohexyl	
31		Lactonization			Substrate (0.2 mmol), Pd(OAc) ₂ (5.0 mol%), Ac-Gly-OH (15 mol%), PhI(OAc) ₂ (2.0 equiv.), KOAc (2.0 equiv.), ^t BuOH, 80 °C, 12 h. 28 Examples; Yield: 19-94% R ¹ & R ² = Alkyl, alkoxy, halogen, COOEt, CF ₃	346
32		Lactonization	R ¹ CHO		Substrate (0.1 mmol), aldehyde (0.2 mmol), [Cp*RhCl ₂] ₂ (8 mol%), AgOTf (40 mol%), Ag ₂ CO ₃ (0.4 mmol), dioxane, 150 °C, 48h, argon. 19 Examples; Yield: 8-81% R= Me, OMe R ¹ = 3-NO ₂ C ₆ H ₄ , 4- & 2-CF ₃ C ₆ H ₄ , 3,5-(CF ₃) ₂ C ₆ H ₄	347

33		Lactonization	-		<p>Substrate (1 equiv.), K_2PtCl_4 (10 mol%), $CuCl_2$ (3.0 equiv.), H_2O (0.01 M), 150 °C, 24 h.</p> <p>$n=0, 1$</p> <p>$m=0, 1$</p> <p>9 Examples; Yield: 20-65%</p> <p>R= Alkyl</p>	325
34		Intramoleculare lactonization			<p>Substrate (1 equiv.), $Pd(OAc)_2$ (10 mol%), (M,S,S)-<i>i</i>-Pr-SPRIX (1 mol%), <i>p</i>-benzoquinone (2.0 equiv.), CH_2Cl_2, 25 °C, 60 h.</p> <p>12 Examples; Yield: 56-98 %</p> <p>$R^1 = Ph, Bn, alkyl$</p> <p>Some specific example with a different substituted double (e.g. Ph)</p>	348

Carboxylic Esters

In 1995, first alkylation reactions on aromatic and hetero-aromatic esters were reported by Trost (Table 14, Entry 1)³⁴⁹ and Kakiuchi (Table 14, Entry 2)³⁵⁰ *et al.*, using a $\text{RuH}_2(\text{CO})(\text{PPh}_3)_3$ complex in toluene at reflux conditions for 24. Kakiuchi's procedure was limited to fluoro and tri-fluoro substituted aromatic systems, with exception of two additional presented transformations, using a thiophene carboxylic ester or a lactone. The alkylation established by Trost was demonstrated on different cyclic alkenes containing an ester or ketone directing group combined with alkoxy or alkylsilanes under well established conditions (e.g Murai type reaction) (Table 15, Entry 7).³⁵¹ This method was also extended to the addition of styrene (Scheme 12, left) as well as for a regioselective alkenylation with 2 equiv of the depicted silylalkyne (Scheme 12, right) in excellent yields of 82%.



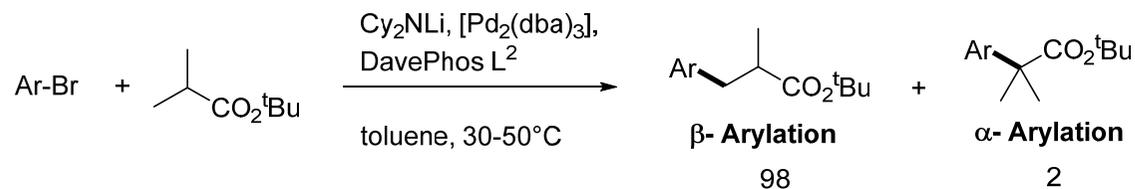
Scheme 12: Early developments in ester- directed alkylation and alkenylation reactions.

The weakly coordinating ester group was used by Padala *et al.*, for highly chemo and diastereoselective ruthenium catalysed alkenylation. During optimization studies, the effects of additives described and most promising results were obtained with $\text{Cu}(\text{OAc})_2 \cdot 3 \text{H}_2\text{O}$ as oxidant, AgSbF_6 under ambient air.³⁵²

An iridium catalysed amidation under very mild conditions (50 °C) with different sulfonyl azides and a broad substrate scope and good functional group tolerance was demonstrated by Kim *et al.* This methodology was also adapted for ketone directed amidation reactions and requires besides a Ir(III) precatalyst also AgNTf_2 , HOAc , Li_2CO_3 for generation of the active, positively charged catalyst to promote the regioselective *ortho* amidation (Table 14, Entry 6).³⁵³

Besides this amidation reaction only a few examples for carbon-heteroatom bond formation reactions (e.g. halogenation³⁵⁴ or hydroxylation³⁵⁵) are published. A highly efficient *ortho* hydroxylation using a mixture of trifluoro-acetic acid and trifluoro-acetic anhydride (TFA/TFAA) and palladium(II) was described for a broad range of starting materials such as aryl ketones, benzoates, benzamides, acetanilides and sulfamides. During optimization studies, the effect of the ratio between TFAA and TFA was evaluated due to reaction speed as well as their role in the catalytic cycle. Most suitable ratio TFA/ TFAA (9:1) showed fast consumption of the starting material and serves also as the required oxygen source (Table 15, Entry 9).³⁵⁵ Furthermore, the group of Rao demonstrate a hydroxylation procedure for a broad range of easily accessible ethyl benzoates (32 examples) using TFA/ TFAA with similar conditions except the catalyst, in this case $[\text{RuCl}_2(p\text{-cymene})]_2$ promotes the oxygenation reaction (Table 14, Entry 10).³⁵⁶

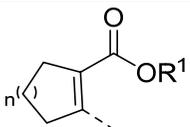
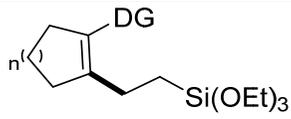
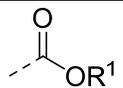
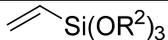
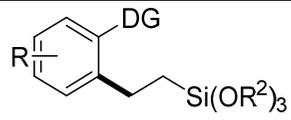
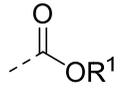
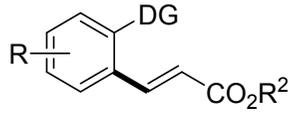
In 2012, a novel carboxylic ester directed β -arylation was published by the group of Boudoin. Especially the effect of the aryl-bromide structure on the β/α selectivity for the arylation of tert-butyl isobutyrate should be underlined. Using *ortho* fluoro-aryl bromid, perfect β/α selectivity of 98/2 was obtained (Scheme 13).

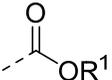
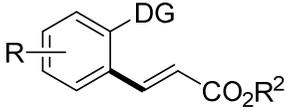
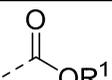
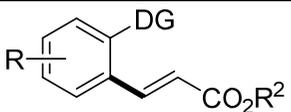
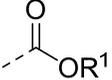
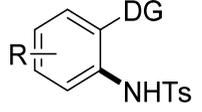
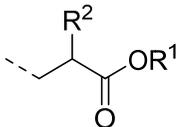
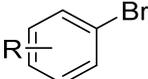
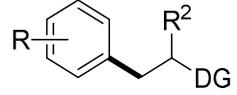


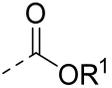
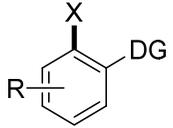
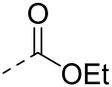
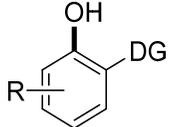
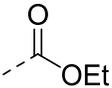
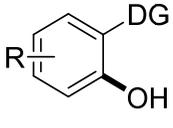
Scheme 13: Ligand- controlled regioselective arylation of C(sp³) centers.

To control the selectivity due to β/α arylations, several different ligands were tested and depending on the structure, the conversions were improved as well as the selectivity. In contrast, *meta*-fluoro or *para*-fluoro substituted aryl bromides showed mixture of both possible products (Table 14, Entry 7).^{357, 358}

Table 14: Ester- directing groups

Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
1		Alkylation			Substrate (1 equiv.), alkene (1.2-4 equiv.), RuH ₂ (CO)(PPh ₃) ₃ (5 mol%), toluene, reflux. 9 Examples; Yield: 19-92 % R ¹ = Me R ² = Ph, SiR ₃	349
2		Alkylation			Substrate (2 mmol), vinylsilane (10 mmol), RuH ₂ (CO)(PPh ₃) ₃ (0.12 mmol), toluene, 135 °C, 249 Examples, Yield: 42-97% R= F or CF ₃ R ¹ = Me, Et R ² = Me, Et	350
3		Alkenylation			Substrate (0.2 mmol), acrylate (0.4 mmol), [RhCp*Cl ₂] ₂ (2.5 mol%), AgSbF ₆ (10 mol%), Cu(OAc) ₂ ·2H ₂ O (20 mol%), DCE, 110 °C, 12 h. 23 Examples; Yield: 3- 72% R= Me, OMe, OH, halogen R ¹ = Alkyl, Bn R ² = Alkyl	359

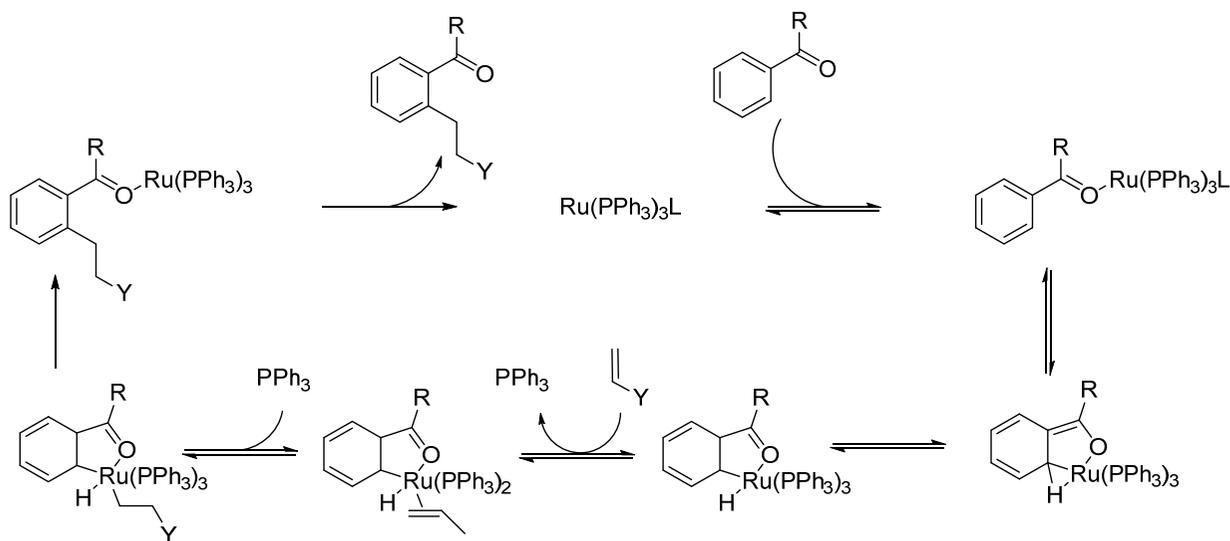
4		Alkenylation			Substrate (1 equiv.), acrylate (1 equiv.), [RuCl ₂ (<i>p</i> -xymene)] ₂ (3 mol%), AgSbF ₆ (20 mol%), Cu(OAc) ₂ (30 mol%), DCE, 100 °C, 12 h. 15 Examples; Yield: 41-89 % R= OMe, OH, halogen R ¹ = Alkyl R ² = Alkyl, halogen	352
5		Alkenylation			Substrate (0.5 mmol), acrylate (1.0 mmol), [RuCl ₂ (<i>p</i> -cymene)] ₂ (5 mol%), AgSbF ₆ (40 mol%), Cu(OAc) ₂ ·H ₂ O (1.0 mmol), DCE, 100 °C, air, 16 h. 14 Examples; Yield: 48-68 % R= Me, OMe R ¹ = Alkyl R ² = Alkyl	360
6		Amidation	R ₂ SO ₂ N ₃		Substrate (0.1 mmol), azide (1.0 equiv.), [IrCp*Cl ₂] ₂ (4 mol%), AgNTf ₂ (16 mol%), HOAc (15 mol%), Li ₂ CO ₃ (15 mol%), DCE, 50 °C, 12 h. 16 Examples; Yield: 51-99% R ¹ = Alkyl, cyclopropyl, lactones, Bn R ₂ SO ₂ N ₃ = NHTs, NHSO ₂ Me, NHSO ₂ CH ₂ C ₆ H ₅	353
7		β Arylation			Substrate (1.6 equiv.), aryl bromide (1 equiv.), [Pd ₂ (dba) ₃] (5 mol%), Cy ₂ NLi (1.7 equiv.), Davephos (10 mol%) toluene, 110 °C. 21 Examples, Yield: 61-81% R= Me, OMe, halogen, CF ₃ R ¹ = Alkyl, Bn R ² = Me, CF ₃ , NBn ₂	357, 358

8		Halogenation	NCS/ NBS		Substrate (1 equiv.), Pd(OAc) ₂ (1.1 equiv.), NCS or NBS (1.0-6.0 equiv.), TfOH, DCE, Na ₂ S ₂ O ₈ , 60-90 °C. 26 Examples; Yield: 36-85% R= Me, halogen, NO ₂ R ¹ = Alkyl	³⁵⁴
9		Hydroxylation	TFA/TFAA		Substrate (1 equiv.), Pd(OAc) ₂ (5 mol%), TFA/TFAA (9:1), oxidants (2 equiv.) (e.g. K ₂ S ₂ O ₈), r.t-50 °C. 6 Examples; Yield: 36-82 % R= Me, OMe, halogen	³⁵⁵
10		Hydroxylation	TFA/TFAA		Substrate (1 equiv.), [RuCl ₂ (<i>p</i> -cymene)] ₂ (2.5 mol%), Selectfluor (1.1 equiv.), TFA/TFAA (7:3), 80 °C. 32 Examples; Yield: 7-93 % R= Me, OMe, halogen, CF ₃ , COOMe	³⁵⁶

Ketones

The carbonyl group in ketones was historically amongst the first directing groups to be used in C-H activation chemistry. Over the last years, several ketone directed C-H functionalizations were reported for a broad substrate scope of sp^2 C-H bonds³⁶¹ except of some specific examples (Table 15, Entry 9).^{362, 363} Ruthenium proved to be especially well suited for ketone directed C-H activation reactions. As can be seen in Table 15, most example take advantage of ruthenium catalysts followed by rhodium as the second most frequently applied metal. Palladium³⁶⁴, has been used successfully only in a handful of examples.

Already in 1993, pioneering work for ketone directed alkylations was published by Murai *et al.* (Table 15, Entry 7)³⁵¹ In this landmark contribution, the first highly efficient and selective carbon-hydrogen cleavage with a simultaneous C-C bond formation mediated by a ruthenium complex on different aromatic ketones (e.g. naphthyl, furan, thiophen) with a mono and disubstitued olefines was shown. (Scheme 14).



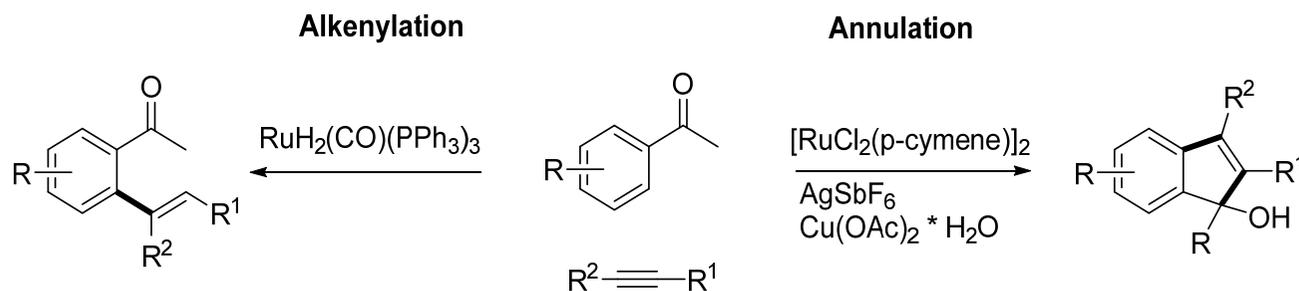
Scheme 14: Proposed mechanism of carbonyl-directed C-H functionalization.

The mechanism proposed in this paper served as guideline for many more contributions to come, and can be considered as one of the most important starting points for the field of C-H activation chemistry, as we experience it today.^{365, 366} It was proposed, that the carbonyl function first precoordinates the metal catalyst, in this case a ruthenium species, which brings it into a position in close proximity of the α -C-H bond next to the ketone function. This allows C-H insertion of Ru into the C-H bond. Basically, the majority of directed C-H activation reactions rely on this type of strategy. In this early example of Murai, olefin insertion and reductive elimination delivered the α -alkylated ketones, the final products of the reported transformation. The reaction was performed with $aRuH_2(CO)(PPh_3)_3$ pre-catalyst, which was reduced to the active Ru(0) in toluene at 135 °C. Further improvements towards reduced reaction temperature (r.t. to 40 °C) and mechanistic studies were published in 2010.³⁶⁵

Independently, the groups of Chaudret (Table 15, Entry 10)³⁶⁷ and Leitner (Table 15, Entry 9)³⁶³ presented optimized alkylation protocols at room temperature catalysed *via* athermolabile $\text{RuH}_2(\text{H}_2)(\text{PCy}_3)_2$ catalyst for aromatic ketones with ethylene. An Ru(II) promoted *ortho* alkylation with an unusual coupling partner, namely maleimides at high temperature (120 °C) with 4 equiv. of water to generate 3-arylated succinimide derivatives in excellent yields (96%) was published (Table 15, Entry 18).³⁶⁸

In 1995, the first catalytic addition of an inactive aromatic C-H bond to a triple bond catalysed by $\text{Ru}(\text{H})_2(\text{CO})(\text{PPh}_3)_3$ in toluene at 135 °C was reported with moderate to good regioselectivity (E/Z= 5/1- 16/1) (Table 15, Entry 4).³⁶⁹ Besides different coupling reagents, such as symmetric or asymmetric acetylenes and different vinylsilanes also furan or thiophen was shown as model substrates. An alkenylation protocol to install fluorine scaffolds *via* perfluoro-alkenylation, mediated by 1 mol% $[(\text{RhCp}^*\text{Cl}_2)_2]$ was presented for cyclic and acyclic aromatic ketones (Table 15, Entry 5).³⁷⁰ In the proposed mechanism, the final β -hydrogen elimination exclusively gives the E isomer of perfluoroethyl acrylate derivatives. In contrast to the well studied Murai type alkylation, which provides linear products, in 2014 a Ir promoted alkene- hydroarylation to generate disfavored branched compounds was published (Table 15, Entry 22).³⁷¹ The selectivity towards the C-C bond forming with the internal carbon of styrene is controlled by the ligand (e.g. $\text{d}^{\text{F}}\text{ppb}^{\text{c}}$) and the styrene loading (coupling reagent) was reduced during optimization studies from 450 mol% to 200 mol% to gave exclusively the branched products.

The effect of non-coordinating anions (e.g. AgSbF_6 , KPF_6) for ruthenium catalysed annulation reactions is depicted in Scheme 15 (Table 15, Entry 28-30).³⁷²⁻³⁷⁴ The addition of AgSbF_6 is required, to increase the activity of the rhodium catalyst by removing the chloride ligands $[(\text{RhCp}^*\text{Cl}_2)_2]$ (Table 15, Entry 28).⁶⁸ Furthermore to favour the ring closure reaction, the addition of a $\text{Cu}(\text{OAc})_2$ as an oxidant as well as the solvent are crucial, to avoid the well-known alkenylation reaction of aromatic ketones with alkynes.



Scheme 15 Ketone directed alkenylation and annulation controlled by the catalyst.

In 2011, Patureau *et al.* presented a novel annulation process to synthesize indenols and fulvenes depending on the substrate structure involved an α, γ dehydration step (loss of a H_2O) or non-dehydrative reaction progress (Table 15, Entry 28).³⁷²

In order to avoid several bottlenecks (e.g. regioselectivity) of β -functionalization, a selective Pd- catalyzed arylation using aryl iodides with excellent functional group tolerance at the β -position of cyclic or acyclic ketones was reported (Table 15, Entry 24).³⁷⁵ The selective arylation in β -position was obtained by a Pd promoted ketone dehydrogenation followed by the formation of an Pd(II)-enolate, a β -H elimination and finally a reductive elimination for catalyst reactivation are part of the catalytic cycle to end up at the regioselective product molecule. Furthermore, a rhodium catalysed β alkylation of 4-phenyl-3-buten-2-one utilizing diethylamine as an chelation assistant tool to give β , γ unsaturated ketones in 2:1 ratio of E/Z isomers (Table 15, Entry 12).³⁷⁶ Key step of this amine assisted functionalisation is the formation of an dienamine intermediate by the condensation of α,β - unsaturated ketone and diethylamine. The active rhodium complex is then coordinating and reductive elimination followed by acidic hydrolysis, which yields in the final product.

A ketone directed C-H activation for a enantioselective hydroarylativ and hydrovinyllative cyclizations were presented by the group Shibata (Table 15, Entry 34).³⁷⁷ They also stated a possible mechanism for the presented cyclization, which follows a (1) directed C-H activation of an enone, (2) a hydorrhodation of the diyne or enyne and (3) intramolecular carborrhodation followed by the generation of the thermodynamically favoured product.

Ketone directing groups have not only been applied in C-C bond forming reactions but also in C-heteroatom bond formations. For example, ruthenium or palladiumcatalysed hydroxylation,^{364, 370, 378} amination³⁷⁹, as well as halogenation.³⁸⁰

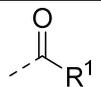
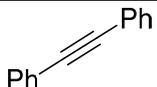
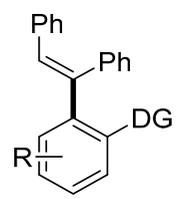
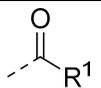
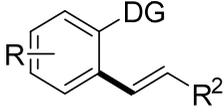
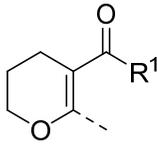
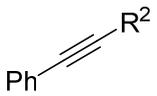
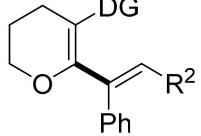
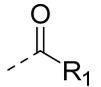
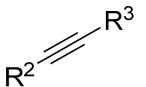
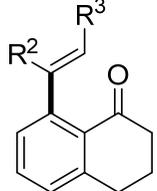
To install a nitrogen containing functional group on an aromatic system, *ortho* amidation procedures by sulfonyl azides were studied in presence of a $\text{RuCl}_2(p\text{-cymene})_2$ (Table 15, Entry 19- 21).³⁸¹⁻³⁸³ This methodology was adapted to broad substrate scope, do not require external oxidants and only nitrogen is generated as byproduct. Another opportunity for direct C-heteroatom formation, is described for benzophenones *via* $\text{Pd}(\text{OAc})_2$ catalyzed mono- or di-hydroxylation reactions. In 2012, the first ketone directed mono- selective arene oxidation using $\text{PhI}(\text{OTFA})_2$ as oxidant in DCE was presented (Table 15, Entry 35).³⁷⁸ The protocol was extended to substituted benzophenones and the final product is formed after aqueous work up of 2-trifluoro-acetoxybenzophenone with perfect regioselectivity. Only tolyl-phenylketone was described to generate the dihydroxylated product.

Another direct hydroxylation protocol to synthesize *ortho*- acylphenols by $\text{Pd}(\text{TFA})_2$ combined with the oxidant (BTI: bis(trifluoroacetoxy)iodo]benzene) at low temperature was reported by the group of Dong (Table 15, Entry 36).³⁶⁴ For benzophenone derivatives, both electron neutral and electron rich aromatic systems are di-hydroxylated and for unsymmetrical benzophenones a mono-selectivity trend towards more electron rich aromatic rings is reported.

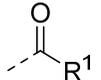
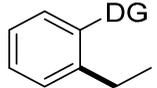
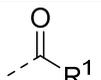
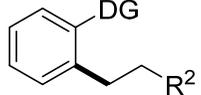
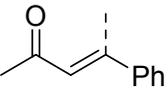
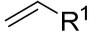
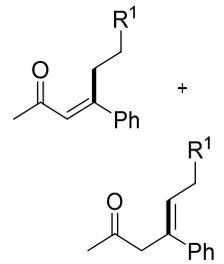
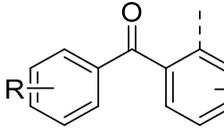
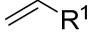
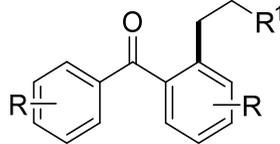
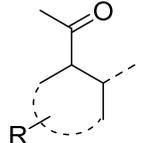
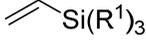
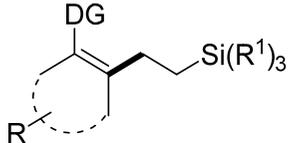
A ketone or ester directed hydroarylation catalysed via inexpensive CoBr_2 and a bidendate phosphine complex (e.g. dppp or dppe) represents a novel protocol to prepare biologically relevant scaffolds containing an exocyclic double bond. During the catalytic cycle, Co(II) is reduced by Zn dust to Co(I), which promotes the oxidative cyclization of 1,6 enynes. Finally the rate determine step, a reductive elimination gave access to functionalized pyrrolidines and dihydrofurans by an atom efficient synthetic process at 40 °C (Table 15, Entry 33).³⁸⁴ Additionally the reaction progress is limited to chlorinated solvents (DCM or DCE), only low yields were obtained in dioxane, THF or toluene. Furthermore, CoI_2 or CoCl_2 combined with different ligands decreasing the activity towards hydroarylativ cyclization.

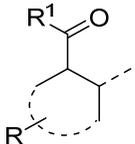
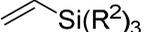
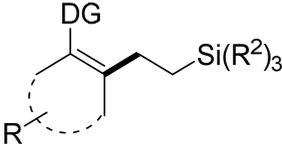
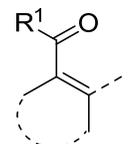
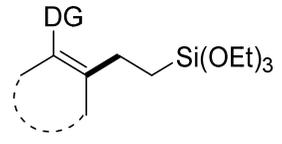
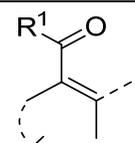
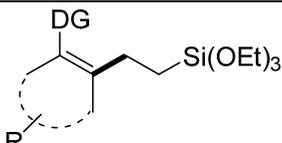
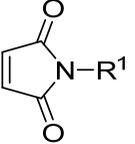
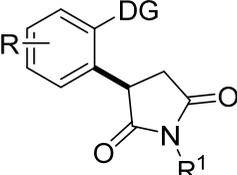
The groups of Shi and Cheng disclosed independently and simultaneously an identical protocol for the synthesis of fluorenones from benzophenones *via* oxidative dual C-H activation (Table 15, Entry 38 & 39).^{385, 386} Both groups also presented a plausible mechanism with the rate determining step, the formation of a six-membered palladium complex after double C-H activation. Finally, a reductive elimination leads to the target molecules and the catalyst is recycled with Ag₂O.

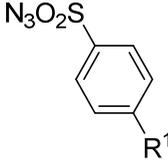
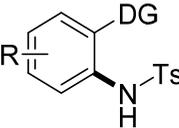
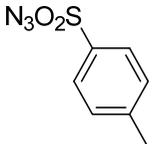
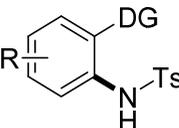
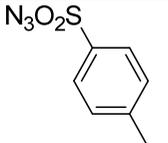
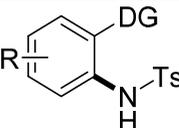
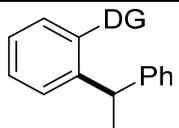
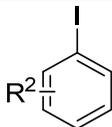
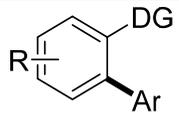
Table 15: Ketone directing groups

Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
1		Alkenylation			Substrate (2 equiv.), alkyne (1 equiv.), [Ir[cod] ₂] ₂ BF ₄ (5 mol%), rac-BINAP (5 mol%), DCE, reflux, 20 h. 8 Examples; Yield: 59-99% R= Me, OMe, CF ₃ R ¹ = Alkyl	³⁸⁷
2		Alkenylation			Substrate (1 mmol), alkene (5-6 mmol), [RuCl ₂ (<i>p</i> -cymene)] ₂ (2 mol%), AgSbF ₆ (10 mol%), Cu(OAc) ₂ ·H ₂ O (25 mol%), DCE, 110 °C, 12 h, under air. 19 Examples; Yield: 55-89 % R= Me, OMe, halogen, COOMe R ¹ = Alkyl; R ² = Me, OEt, alkyl, aryl, COOR (alkyl)	³⁸⁸
3		Alkenylation			Substrate (2 mmol), RuH ₂ (CO)(PPh ₃) ₃ (0.12 mmol), toluene, 135 °C. 3 Examples; Yield: 56-96% R ¹ =Alkyl R ² = Ph, SiMe ₃	³⁸⁹
4		Alkenylation			Substrate (2 mmol), alkyne (4 mmol), RuH ₂ (CO)(PPh ₃) ₃ (0.12 mmol), toluene, 135 °C. 9 Examples; Yield: 20-99% E/Z= 5/1-16/1 R ¹ = Alkyl; R ¹ & R ² = Alkyl, SiMe ₃ Heterocycles tolerated	³⁶⁹

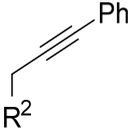
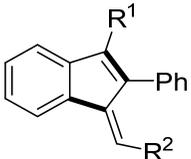
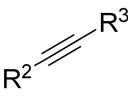
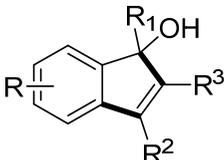
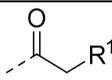
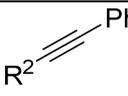
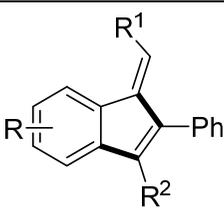
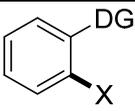
5		Alkenylation			Substrate (1 equiv.), alkene (1.5 equiv.), [(RhCp*Cl ₂) ₂] (1.0 mol%), AgSbF ₆ (20 mol%), Cu(OAc) ₂ (1.0 equiv.), ^t Amyl-OH, 100 °C. 16 Examples; Yield: 70-96% R= Alkyl, alkoxy, halogen, di-substituted R ¹ = CH ₂ CF ₃ , CH ₂ CF ₂ CF ₃	³⁷⁰
6		Alkenylation/ Cyclization			Substrate (0.2 mmol), acrylate (0.5 mmol), Cp*Rh(CH ₃ CN) ₃ (SbF ₆) ₂ (5 mol%), AgOAc (1.0 equiv.), H ₂ O, DCE, 130 °C, 48 h. 20 Examples; Yield: 21-78% R= Me, OMe, halogen; R ¹ = Me; R ² = Alkyl	³⁹⁰
7		Alkylation			Substrate (2 mmol), alkene (2-12 mmol), RuH ₂ (CO)(PPh ₃) ₃ (0.04 mmol), toluene, 125 °C, 0.2-90 h. 13 Examples; Yield: 66-99% R= Me R ¹ = SiMe ₃ , Si(OEt) ₃ , aryl, ^t Bu Heterocycles tolerated	³⁵¹
8		Alkylation			Substrate (1 mmol), alkene (2 mmol), RuH ₂ (CO)(PPh ₃) ₃ (2 mol%), toluene, r.t.-40 °C, 48 h. 8 Examples; Yield: 74-96% R= Me; R ¹ = Alkyl	³⁶⁵
9		Alkylation	Ethylene		Substrate (0.4 mmol), ethylene (1 g, 30 bar), RuH ₂ (H ₂) ₂ (PCy ₃) ₂ (0.04 mmol), toluene, 23 °C. 5 Examples; Yield 22-100% R= Me, OMe, Cl, CF ₃	³⁶³ , ³⁹¹

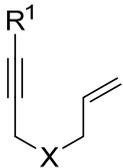
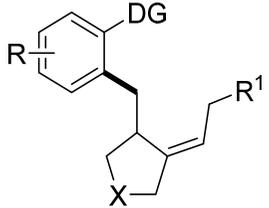
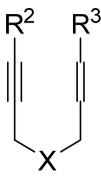
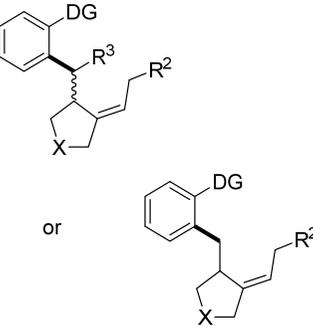
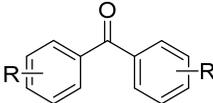
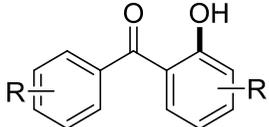
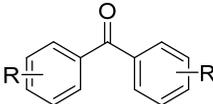
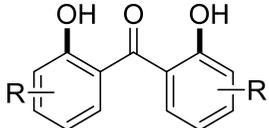
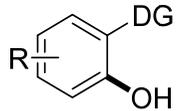
10		Alkylation	Ethylene		Substrate (10 equiv.), ethylene (800 equiv.), RuH ₂ (H ₂) ₂ (PCy ₃) ₂ (1 eq), pentane, 18 °C. 7 Examples; Yield: depending on the temperature R ¹ = Me, Ph	³⁶⁷
11		Alkylation			Substrate (0.324 mmol), alkene (0.972 mmol), [Rh(PPh ₃) ₃ Cl] (5 mol%), PhCH ₂ NH ₂ (0.162 mmol), toluene, 150 °C, 6 h. 10 Examples; Yield: traces-95% R ¹ & R ² = Alkyl	³⁹²
12		Alkylation			Substrate (1 mmol), alkene (10 mmol), RhCl(PPh ₃) ₃ (0.05 mol%), PhCO ₂ H (0.1 mmol), sec-amine (0.5 mmol), toluene, 150 °C. 11 Examples; Yield: 6-99% R ¹ = Alkyl, cyclohexyl, Mesilane	³⁷⁶
13		Alkylation			Substrate (1 equiv.), alkene (1 equiv.), RuH ₂ (CO)(PPh ₃) ₃ (5 mol%), cyclohexan, 120 °C. 10 Examples; Yield: 10-99% 5 Examples; Yield: 35-91 % (acetophenone derivatives) R= OMe, CF ₃ ; R ¹ = SiMe ₃ , C ₃ H ₇ , OEt, cyclopentene	³⁹³
14		Alkylation			Substrate (1 mmol), vinyl silane (2 equiv.), [RuCl ₂ (<i>p</i> -cymene)Cl ₂] ₂ (2.5 mol%), NaHCO ₂ (30 mol%), PPh ₃ (15 mol%), toluene, 140 °C. 10 Examples; Yield: 70-100 % R= Me, OMe, halogen; R ¹ = Me, OEt Heterocycles tolerated	³⁹⁴

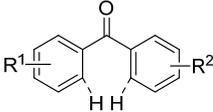
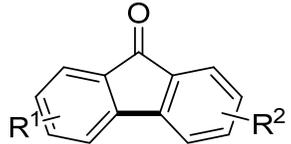
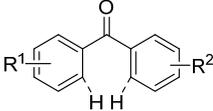
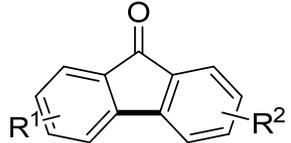
15		Alkylation			Substrate (1 mmol), vinyl silane (2 equiv.), [RuCl ₂ (<i>p</i> -cymene)Cl ₂] ₂ (2.5 mol%), NaHCO ₂ (30 mol%), PPh ₃ (15 mol%), toluene, 140 °C. 10 Examples; Yield: 21-100 % R= Me, OMe, halogen; R ¹ = Alkyl, Ph, cyclopropyl R ² = Me, OMe, OEt	395
16		Alkylation			Substrate (1 mmol), vinyl silane (2 mmol), [RuCl ₂ (<i>p</i> -cymene)] ₂ (5 mol%), P(Ar) ₃ (10-15 mol%), NaOCOH (30 mol%), ⁱ PrOH, co solvent, 80 °C. 14 Examples; Yield: 49-91% R ¹ = Cy, Et	396
17		Alkylation			Substrate (1 mmol), vinyl silane (2 mmol), RuCl ₃ ·H ₂ O (4 mol%), NaHCO ₂ (30 mol%), P(4-CF ₃ C ₆ H ₄) ₃ (15 mol%), dioxane, 80 °C, 20 h. 11 Examples; Yield: 54-92% R= Me, OMe, halogen R ₁ = Me, cyclohexanone, (1-ethoxyethyl)-benzene Heterocycles tolerated	397
18		Alkylation (Maleimides)			Substrate (0.3 mmol), maleimide (0.6 mmol), [Ru(<i>p</i> -cymene)Cl ₂] ₂ (7.5 mol%), AgSbF ₆ (30 mol%), Cu(OAc) ₂ ·H ₂ O (1.5 equiv.), AcOH (10.0 equiv.), H ₂ O (5.0 equiv.), DCE, 120 °C, argon. 19 Examples; Yield: 54- 90% R= Alkyl, alkoxy, halogen; R ¹ = Bn, Ph, Et	368

19		Amidation			Substrate (1 mmol), azide (1.5 mmol), [RuCl ₂ (<i>p</i> -cymene)] ₂ (5 mol%), AgSbF ₆ (20 mol%), Cu(OAc) ₂ ·H ₂ O (50 mol%), DCE, 100 °C. 17 Examples; Yield: 8-94% R= Alkyl, alkoxy, halogen R ¹ = Alkyl, NO ₂ , CF ₃ , halogen, Bn	381
20		Amidation			Substrate (2 equiv.), azide (0.2 mmol), [RuCl ₂ (<i>p</i> -cymene)] ₂ (4 mol%), AgNTf ₂ (16 mol%), NaOAc (20 mol%), DCE, 80 °C, 12 h. 20 Examples; Yield: 40-97%: R= Me, OMe, halogen; R ¹ = Alkyl, Ph	382
21		Amidation			Substrate (0.3 mmol), azide (0.6 mmol), [RuCl ₂ (<i>p</i> -cymene)] ₂ (2.5 mol%), AgSbF ₆ (10 mol%), Cu(OAc) ₂ (30 mol%), DCE, 80 °C. 20 Examples; Yield: 30-85% R= Me, OMe, halogen R ¹ = Alkyl, cyclopropyl, cyclopentyl, Ph	383
22		Arylation			Substrate (100 mol%), alkene (450 mol%), [Ir(cod) ₂]BARF (5 mol%), d ^F ppb (5 mol%), dioxane, 100-120 °C, 24-48 h. 5 Examples; Yield: 18-84% R ¹ = Ph, alkyl& amides	371
23		Arylation			Substrate (1 mmol), aryl iodide (3 mmol), Pd(OAc) ₂ (10 mol%), Ag ₂ O (1.0 equiv.), TFA, 120 °C, 20 h. 11 Examples; Yield: 23-92% R= Alkyl, halogen R ¹ = Alkyl, Ph R ² = OMe, COOEt, NO ₂	398

24		Arylation			Substrate (1 mmol), aryl iodide (0.4 mmol), Pd(TFA) ₂ (0.04 mol%), P(<i>i</i> -Pr) ₃ (0.08 mol%), AgTFA (0.8 mmol), HFIP/dioxane 1:1, 80 °C, 12 h. 25 Examples; Yield: 32-91% R= Me, OMe, RCOR, RCOH, halogen	375
25		Arylation			Substrate (2 mmol), phenylboronate (1 mmol), RuH ₂ (CO)(PPh ₃) ₃ (0.02 mol%), toluene, reflux. 15 Examples; Yield: 56-92% R= OMe, F, CF ₃ ; R ¹ = Alkyl; R ² = Me, OMe, NMe ₂ , F, CF ₃	399
26		Arylation			Substrate (1 mmol), aryl bromide (1-7.5 mmol), Pd(PPh ₃) ₃ (0.01-0.005 mmol), Cs ₂ CO ₃ (3-5 mmol), <i>o</i> -xylene, N ₂ , 160 °C. 25 Examples; Yield: 18-68% R= OMe, Cl R ¹ & R ² = OMe, Cl	400
27		Arylation and Cyclization			Substrate (1 mmol), aryl iodide (3 mmol), Pd(OAc) ₂ (10 mol%), Ag ₂ O (1.0 equiv.), TFA, 120 °C, 20 h. 9 Examples; Yield: 60-78% R= Alkyl, halogen R ¹ = ⁱ Pr, cyclohexyl and cyclopentyl R ² = COOEt, NO ₂	398
28		Cyclization			Substrate (1 mmol), phenome/alkyne (1:1.2 or 1.2:1), [RhCp*Cl ₂] ₂ (0.5 mol%), AgSbF ₆ (2 mol%), Cu(OAc) ₂ (2.1 equiv.), PhCl, 120 °C, 16 h. 10 Examples; Yield: 49-90% R= Br, CF ₃ ; R ¹ = Alkyl, Ph, 3,5-(CF ₃)C ₆ H ₃	372

					R ² =Ph, alkyl	
29		Cyclization			Substrate (1 mmol), phenome/ alkyne (1:1.2 or 1.2:1), [RhCp*Cl ₂] ₂ (2.5 mol%), AgSbF ₆ (10 mol%), Cu(OAc) ₂ (2.1 equiv.), 1,4-dioxane, 140 °C, 16 h. 6 Examples; Yield: 51-80% R ₁ = Ph, anisol R ² = Me, Ph	372
30		Cyclization			Substrate (1 mmol), alkyne (1.2 mmol), [RuCl ₂ (<i>p</i> -cymene)] ₂ (2 mol%), AgSbF ₆ (8 or 20 mol%), Cu(OAc) ₂ ·H ₂ O (25 mol%), DCE, 120 °C. 21 Examples; Yield: 69-94% R= Me, OMe, halogen; R ² = Ph; R ³ = Alkyl, SiMe ₃ dehydration product with Ag > 8 mol%	373, 374
31		Cyclization			Substrate (1 mmol), phenome/ alkyne (1:1.2 or 1.2:1), [RhCp*Cl ₂] ₂ (2.5 mol%), AgSbF ₆ (10 mol%), Cu(OAc) ₂ (2.1 equiv.), 1,4-dioxane, 140 °C, 16 h. 8 Examples; Yield: 40-70% R ¹ = Me; R ² = Ph, alkyl	372
32		Halogenation	NXS		Substrate (1 mmol), NXS (1.6 equiv.), [RhCp*Cl ₂] ₂ (2.5 mol%), AgSbF ₆ (10 mol%), PivOH (1.1 equiv.), 1,2-DCE, 60-120 °C, 16-48 h. 7 Examples; Yield: 49-78% R ₁ = Alkyl, OEt; X= Br, I	380

33		Hydroarylativative Cyclization			Substrate (0.32 mmol), enyne (0.30 mmol), CoBr ₂ (5 mol%), dppp (5 mol%), Zn (10 mol%), ZnI ₂ (20 mol%), CH ₂ Cl ₂ , 40 °C, 2 h. 18 Examples; Yield: 71-94% R= Me, OMe, halogen, CF ₃ ; R ¹ = Aryl, Ph, thiophen X= O, NTs, C(CO ₂ Me) ₂	384
34		Hydroarylativative Cyclization			Substrate (3 equiv.), diyne (1 equiv.), [Rh(biphep)]BF ₄ (5 mol%), CH ₂ Cl ₂ , r.t., 30 min. 7 Examples; Yield: 55-99% R ¹ = Me, Ph R ² & R ³ = Me, Ph X= NTs, C(CO ₂ Bn) ₂ , [C(CO ₂ Et) ₂] ₂	377
35		Hydroxylation	TFA		Substrate (0.5 mmol), Pd(OAc) ₂ (5 mol%), PhI(OTFA) ₂ (1 mmol), DCE, 80 °C, 2 h. 20 Examples; Yield: 70-86% R= Me, OMe, halogen	378
36		Hydroxylation	TFA		Substrate (0.4 mmol), Pd(OAc) ₂ (5 mol%), BTI (2 eq.) or K ₂ S ₂ O ₈ (2 equiv.), TFA, 50 °C. 5 Examples; Yield: 21-77% R= Me, OMe	364
37		Hydroxylation	TFA/TFAA		Substrate (1.0 mmol), [Ru(O ₂ CMes) ₂ (<i>p</i> -cymene)] (1-5 mol%), PhI(OAc) ₂ (1.2 equiv.), TFA/TFAA (3/2), 120 °C. 15 Examples; Yield: 57-83% R= Alkyl, alkoxy, halogen R ¹ = ^t Bu	379

38		Oxidative arylation	-		Substrate (0.2 mmol), Pd(OAc) ₂ (5.0 mol%), Ag ₂ O (1.5 equiv.), K ₂ CO ₃ (2.5 equiv.), TFA, 140 °C, 24 h. 21 Examples; Yield: 28-94% R ¹ & R ² = Me, OMe, OH, halogen	385
39		Oxidative arylation	-		Substrate (1.0 mmol), Pd(OAc) ₂ (10 mol%), Ag ₂ O (1.5 equiv.), TFA, 140 °C, 24 h. 15 Examples; Yield: 68-91% R ¹ & R ² = Me, OMe, OH, halogen	386

Hydroxyl- and Phenol- based derivatives

In general hydroxyl directed C-H functionalization is restricted to the *ortho* position due to the electron-donating ability of the oxygen group. To control the regioselectivity for *meta*- alkenylation, a modified phenol molecule containing a hydrolytic removable CN moiety was published by the group of Yu (Table 16, Entry 17).⁴⁰¹

An asymmetric rhodium catalysed cyclization using several directing groups such as ether, sulfide and sulfoxide groups to synthesize seven or eight membered heterocycles via olefin hydroacylation was reported by the group of Dong (Table 16, Entry 15).⁴⁰² During mechanistic studies they showed the catalytic process contains several steps (C-H bond activation, olefination insertion, and reductive elimination) to perform intramolecular cyclization reactions with controlled regioselectivity, which is highly depending on the catalyst-ligand and the substrate structure.

The group of Yu presented a catalytic system, which consists of Pd(OAc)₂ pre-catalyst, Li₂CO₃ as base and Ph(IOAc)₂ as oxidant with a hydroxyl directing moiety to synthesize dihydrobenzofurans (Table 16, Entry 13).⁴⁰³ A Pd(OAc)₂ pre-catalyst and similar starting materials combined with amino acid ligands promotes a novel carbonylation reaction for the synthesis of 1-isochromanone scaffolds. The optimization of the reaction conditions was limited by decomposition of the Pd(II) to palladium black in the presence of CO. To overcome this obstacle, different amino acid ligands were tested and (+)-menthyl(O₂C)-Leu-OH and elevated temperature of 110 °C gave an increased overall yield of 50% (35 to 85%) (Table 16, Entry 12).⁴⁰⁴

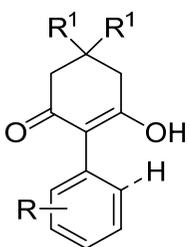
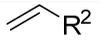
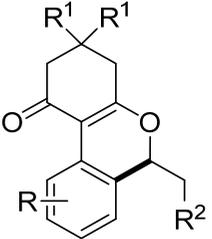
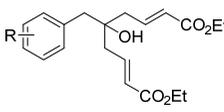
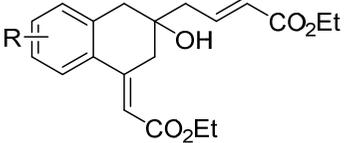
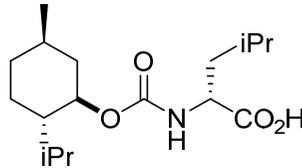
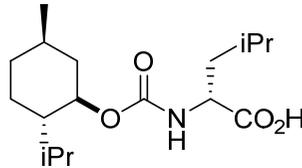
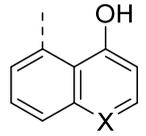
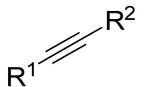
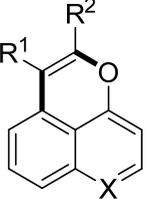
An enantioselective fluorination reaction for a broad range of acyclic alcohols *via* an *in-situ* generation of a boronic acid monoester, which will act as a removable directing group was presented by the group of Toste (Table 16, Entry 14).⁴⁰⁵ After condensation between the boronic acid and the primary alcohol a γ selective fluorination by Selectfluor at r.t. catalysed by S-(AddIP), a phosphate bearing 4-(1-adamantyl)-2,6-diisopropyl BINOL ligand system gives the final products in high yields (94%) and excellent enantioselectivity (up to 94% ee).

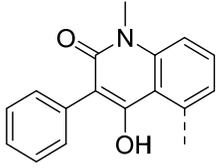
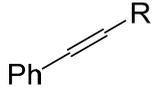
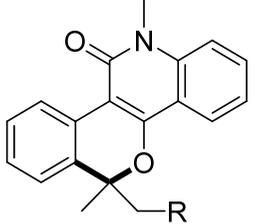
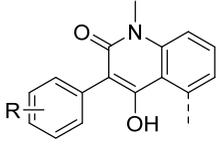
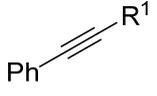
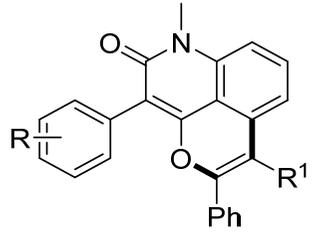
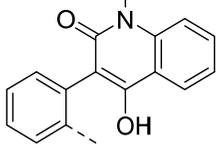
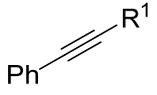
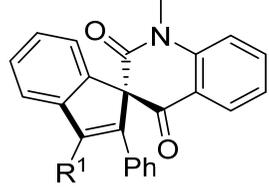
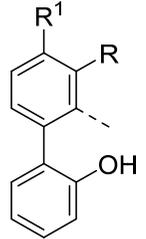
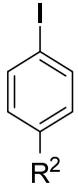
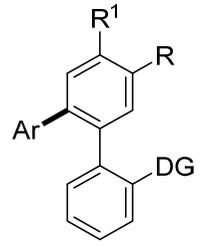
Hydroxy- directed arylation reactions can be divided into three different types (1) an *ortho* arylation catalysed by [RhCl(PPh)₃]₃ with a phosphinite co-catalyst (Table 16, Entry 8 & 9)^{406, 407} or (2) a regioselective arylation on the remote ring strongly influenced from the reaction conditions (Table 16, Entry 7).⁴⁰⁸ Diarylation on the remote ring system was obtained by PdCl₂, Cs₂CO₃ in DMF at 100 °C. In contrast, the mono-arylated compound requires anhydrous conditions by adding a molecular sieve and is promoted by Pd(OAc)₂. (3) An intramolecular arylation *via* Pd(PPh₃)₃, by the insertion of Pd into the C-X (X= Br, I) bond followed by the C-C bond formation reactions another procedure to form a new C-C bond is reported (Table 16, Entry 10).⁴⁰⁹

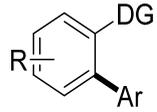
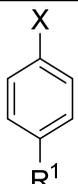
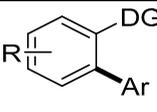
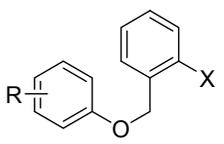
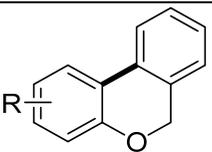
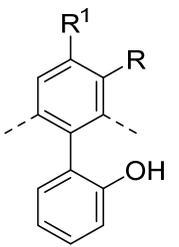
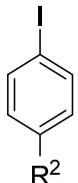
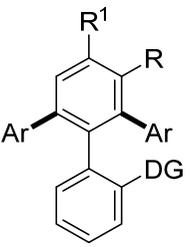
A metal- catalysed oxidative annulation of 2-aryl-3-hydroxy-2-cyclohexenones was reported to provide benzopyrans in good yields up to 78%. During the evaluation of reaction conditions, various pre-catalyst were tested and best results were obtained by Pd(OAc)₂ for electron-deficient alkenes including vinyl ketone. In the case of [RuCl₂(*p*-cymene)]₂ increased yields were obtained with methyl acrylate, *N,N*-dimethylacrylamide and acrylonitrile were determined (Table 16, Entry 1).⁴¹⁰

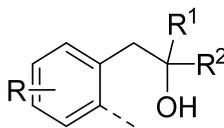
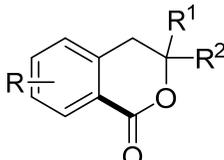
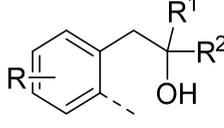
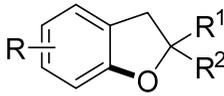
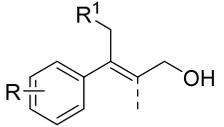
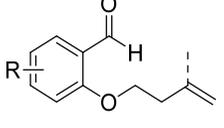
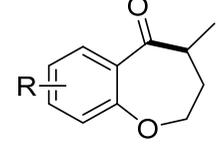
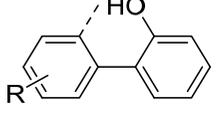
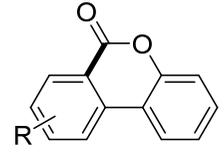
A switchable C-H functionalization of substrate molecules, containing different reactive C-H bonds will give access to a variety of products from the same starting material. In this approach 2-aryl cyclic 1,3-dicarbonyl compounds that contains two position for activation were used and the product selectivity was controlled by the catalyst-ligand structure. A palladium-*N*-heterocyclic carbene complex promotes the oxidative annulation with alkynes to spiroindenes in good yields (87%) within 5h. In comparison, $[\text{RuCl}_2(p\text{-cymene})_2]$ gave in 22h selectively the benzopyran product using $\text{Cu}(\text{OAc})_2 \cdot \text{H}_2\text{O}$ as oxidant in *m*-xylene/ H_2O (10:1) solvent mixture (Table 16, Entry 5 & 6).⁴¹¹

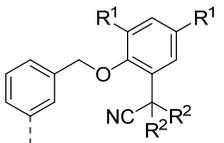
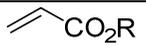
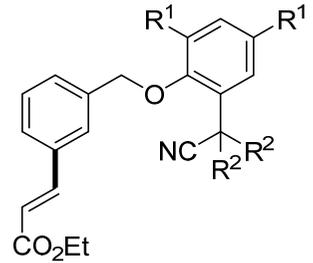
Table 16: Hydroxyl- and phenol- based directing groups

Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
1		Alkenylation/ Cyclization			<p>Substrate (0.5 mmol), alkene (1.5 equiv.), Pd(OAc)₂ (5 mol%), Cu(OAc)₂ (2.1 equiv.), DMF, 120 °C, 2-5 h.</p> <p>[RuCl₂(<i>p</i>-cymene)]₂ (2.5 mol%), Cu(OAc)₂·H₂O (2.1 equiv.), K₂CO₃ (2 equiv.), ¹Amyl-OH, 90 °C.</p> <p>22 Examples; Yield: 45-76%</p> <p>R= Me, F, R¹= Me R²= SO₂Ph, COOMe, CN</p>	410
2		Alkenylation/ Cyclization			<p>Substrate (1 equiv.), Pd(OAc)₂ (10 mol%), L1 (20 mol%), AgOAc (4.0 equiv.), Li₂CO₃ (2.0 equiv.), DCE, 90 °C, 64 h.</p>  <p>L1= </p> <p>11 Examples; Yield: 30-98%</p> <p>dr=91:9</p> <p>R= OMe, Me, CF₃</p>	412
3		Annulation			<p>Substrate (1 mmol), alkyne (0.5 mmol), [RuCl₂(<i>p</i>-cymene)]₂ (2.5 mol%), Cu(OAc)₂·H₂O (1 mmol), <i>m</i>-xylene, 80-110 °C.</p> <p>24 Examples; Yield: 48-81%</p> <p>R¹ & R² = Aryl substituted with Me, CF₃, OMe, halogen X= O, NMe</p>	413

4		Annulation			Substrate (0.5 mmol), Pd (OAc) ₂ (5 mol%), Cu(OAc) ₂ (2.1 equiv.), DMF, 120 °C, 3-15 h. 5 Examples; Yield: 32-86% R= COOMe, COMe, CN, SO ₂ Ph	411
5		Annulation			Substrate (0.5 mmol), [RuCl ₂ (<i>p</i> -cymene)] ₂ (5 mol%), Cu(OAc) ₂ ·H ₂ O (2.1 equiv.), DMF, 90 °C, 1-5 h. 9 Examples; Yield: 32-88% R= Me, OMe, COOMe R¹= Alkyl, OMe, COOMe	411
6		Annulation			Substrate (0.5 mmol), alkyne (1.5 equiv.), PEPPSI-IPr (2.5 mol%), Cu(OAc) ₂ (2.1equiv.), DMF, 120 °C, 2-5 h. 9 Examples; Yield: 45-87% R¹= Alkyl, Ph, aryl	411
7		Arylation			Substrate (1 mmol), aryl iodide (1.2 mmol), Pd(OAc) ₂ (0.05 mmol), Cs ₂ CO ₃ (1.2 mmol), molecular sieves 4 A (200 mg), DMF (5 mL), 100 °C. 8 Examples; Yield: 70-88% R= OMe, NO ₂ R¹= Me R²= OMe	408

8		Arylation			Substrate (1 mmol), aryl halide (1.5 mmol), [RhCl(PPh ₃) ₃] (0.05 mmol), PR ₂ (OAr) (0.15 mmol), Cs ₂ CO ₃ (1.7 mmol) toluene, reflux, N ₂ , 18 h. 13 Examples, Yield: 21-100% R= Alkyl R ¹ = Me, OMe, carbonyl X= Br, Cl	406
9		Arylation			Substrate (1 mmol), aryl halide (1.5 mmol), [RhCl(PPh ₃) ₃] (0.05 mmol), PR ₂ (OAr) (0.15 mmol), Cs ₂ CO ₃ (1.7 mmol), toluene, reflux, 18 h, N ₂ . 22 Examples, Yield: 15-96% R= Alkyl R ¹ = Me, OMe, RCO, NMe ₂ , halogen X= Br, Cl Heterocyclic halides tolerated	407
10		Intramolecular Arylation			Substrate (1 equiv.), Pd(PPh ₃) ₄ (0.2 equiv.), ^t BuOK (3 equiv.), DMA, 95 °C, 2 d. 5 Examples, Yield 90 % R= OH, Me X= Br, Cl	409
11		Diarylation			Substrate (1 mmol), aryl halide (1.2 mmol), PdCl ₂ (0.05 mmol), Cs ₂ CO ₃ (4 mmol), DMF (5 mL), 100 °C. 8 Examples; Yield: 57-87% R ¹ = Me R ² = OMe	408

12		Carbonylation/ lactonization	CO		Substrate (1.0 equiv.), Pd(OAc) ₂ (10 mol%), (+)-Men-Leu-OH (20 mol%), AgOAc (3.0 equiv.), Li ₂ CO ₃ (1.0 equiv.), CO (1 atm), DCM, 110 °C, 48 h. 20 Examples; Yield: 51-94% R= Me, OMe, halogen R ¹ & R ² = Alkyl	404
13		Cyclization/ lactonization			Substrate (0.2 mmol), Pd(OAc) ₂ (0.01 mmol), PhI(OAc) ₂ (0.3 mmol), Li ₂ CO ₃ (0.3 mmol), C ₆ F ₆ , 100 °C, 36 h. 20 Examples; Yield: 42-91% R= Me, OMe, halogen R ¹ & R ² = Alkyl, Ph, Bn, COOR	403
14		Fluorination	Selcetfluor		Substrate (1 equiv.), (S)-AdDIP (10 mol%), Selcetfluor (1.3 equiv.), Na ₂ HPO ₄ (4.0 equiv.), <i>p</i> -tolylboronic acid (1.0 equiv.), MgSO ₄ (40mg/ 0.10 mmol), <i>p</i> -xylene/Etcyclohexane (1:1), 0.1 M, r.t., 16-96 h. 15 Examples; Yield: 47-85% (ee 94%) R= Me, OMe, halogen, CF ₃ R ¹ = Alkyl	405
15		Intramolecular Olefin Hydroacylation			Substrate (1 equiv.), [RH((R,R)-Me-DuPHOS)]BF ₄ (5 mol %), CH ₂ Cl ₂ , r.t., 24 h. 8 Examples; Yield: 80-95% R= Me, OMe, halogen	402
16		Carbonylation - lactonization	CO		Substrate (1 equiv.), [RuCl ₂ (<i>p</i> -cymene)] ₂ (4 mol%); HIPrCl (12 mol%); PivOH (10 mol%); Cs ₂ CO ₃ (3.0 equiv.), mesitylene, 100 °C, CO (ballon), O ₂ (balloon) 15 Examples; Yield: 28-96%	414

					R= Me, OMe, CF ₃ , COOEt, CN, Ac, halogen	
17		Alkenylation			<p>Substrate (0.05 mmol), acrylate (1.5 equiv.), Pd(OPiv)₂ (10 mol%), Ag(OPiv) (3 equiv.), DCE, 90 °C, 18 h.</p> <p>40 Examples; Yield: 4-86 %</p> <p>R= alkyl, Bn</p> <p>R¹ & R²= Alkyl</p>	401

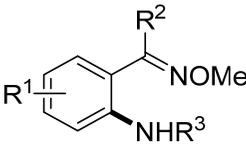
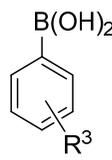
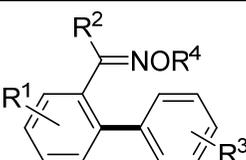
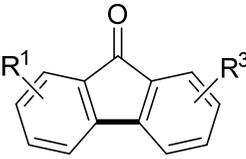
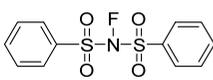
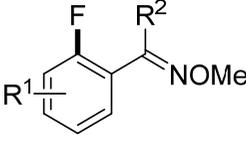
Oxime and Oxime derivatives as directing groups in C-H activation chemistry

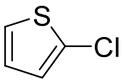
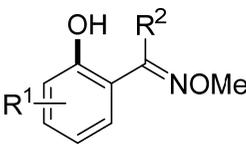
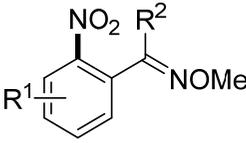
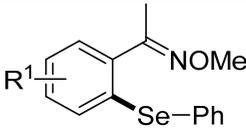
Oxime containing directing groups are manifold and can generally be subdivided in ketoximes, aldoximes and their ethers and esters. In 2012, one of the first rhodium-catalyzed oxidative *ortho*-acylation of aryl ketoxime ethers with aryl- and alkyl aldehydes via C-H bond activation was demonstrated by Yang et al. Noteworthy; the resulting monoacylated products proceeded to a Rh-catalyzed addition of the second *ortho* C-H bond to aldehydes, when highly deficient benzaldehydes are employed as coupling partners. In this case, no mono-acylation products were observed and two C-C bonds were generated simultaneously (Table 17, Entry 1 & 2).⁴¹⁵ Another example for a Rh(III) catalyzed ketoxime ether directed aromatic C-H bond activation is the oxidative coupling to alkenes reported by Tsai et al. This procedure demonstrated the at this time unknown transformation with nonactivated olefins for Rh catalysts (Table 17, Entry 3).⁴¹⁶ Further, it is also substantial to take advantage of the ubiquity of C-H bonds for C-N coupling. The Li group achieved an amidation of arenes bearing chelating groups by applying *N*-arene sulfonated imides as amidation reagents without the need for the addition of a base (Table 17, Entry 4).⁴¹⁷ Another C-N bond formation is realized by applying 1,4,2-dioxazolone as coupling partner. This C-H amidation was published by Park et al. in 2015 (Table 17, Entry 5).⁴¹⁸ The same coupling partner was used in a protocol of the Li group. In this case the applicability to the late stage functionalization of natural products was demonstrated (Table 17, Entry 2).⁴¹⁹ Further, the Fu group were the first, who reported a Rh-catalyzed directed C-H cyanation as a practical method for the synthesis of aromatic nitriles (Table 17, Entry 6).²¹² In 2015 a rhodium(III)-catalyzed coupling of aromatic ketoxime ethers with 2-vinylloxirane via directed C-H activation was described by Wen et al. Remarkable, this procedure contains an allylation and a concomitant epoxide opening (Table 17, Entry 9).⁴²⁰ In 2006 a palladium-catalyzed procedure for an intramolecular amidation via cascade C-H activation/nitrene insertion was published by the Che group (Table 17, Entry 10).⁴²¹ Lou et al. described a palladium catalyzed mild, versatile nitrate promoted C-H bond fluorination in 2014 (Table 17, Entry 13).⁴²² However, versatile functionalizations of the ketoxime ether scaffold were demonstrated. For instance a ligand-promoted Pd-catalyzed hydroxylation (Table 17, Entry 15)⁴²³, a chelation assisted, regioselective nitration (Table 17, Entry 16)⁴²⁴, a direct selenylation of arenes with electrophilic selenenyl chlorides or diselenides (Table 17, Entry 17)⁴²⁵, and even a rhodium catalyzed oxime ether directed heteroarylation was presented. This procedure provides a straightforward access to bi(hetero)aryl scaffolds (Table 17, Entry 14).⁴²⁶ Even the synthesis of highly substituted benzofuranes by activation of a sterically hindered C-H bond has been demonstrated. Benzofurane derivatives, frequently used as building blocks in organic materials, are an important class of heterocycles found in many natural and biologically active molecules. This rhodium(III)-catalyzed C-H activation starts from meta-substituted hydroxybenzenes and alkynes (Table 17, Entry 19).⁴²⁷ The Sanford group reported in 2004 that unactivated sp³ C-H bonds of oxime substrates undergo highly regio- and chemoselective palladium catalyzed oxygenation under acidic conditions with PhI(OAc)₂ as stoichiometric oxidant (Table 17, Entry 20).⁴²⁸ A different example for the application of a hypervalent iodine reagent, is the palladium catalyzed β -arylation of oxime ethers using diaryliodonium salts as key arylation reagent described by Peng et al. (Table 17, Entry 21).⁴²⁹ In 2014 a process applying an unprecious metal was described by the Ellman group. An air-stable cationic Co(III) catalyst for a one-step synthesis of furans by C-H bond additions to aldehydes followed by in situ cyclization and aromatization was demonstrated. This protocol is the first examples of Co(III)-catalyzed additions to aldehydes (Table 17, Entry 24).⁴³⁰ Further, in 2013 a decarboxylative C-H activation in form of an *ortho*-acylation with α -keto acids under ammonium persulfate as a convenient oxidant was described by Kim et al. (Table 17, Entry 1).⁴³¹

Table 17: Ketoxim ether directing groups

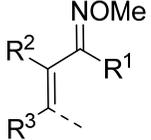
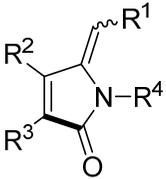
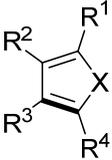
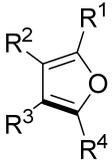
Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
1		Acylation			Substrate (1 eq), aldehyde (4 eq), [Cp*RhCl ₂] ₂ (0.1 eq), AgSbF ₆ (0.4 eq), AgCO ₃ (2.5 eq), DCM (0.2 M), 85 °C, 24 h, highly electron deficient benzaldehyde required 3 examples, 41-60 % yield R: PhCOOMe, PhCHO, PhCH ₃ CO	415
2		Acylation			Substrate (1 eq), aldehyde (2.5 eq), [Cp*RhCl ₂] ₂ (0.05 eq), AgSbF ₆ (0.2 eq), AgCO ₃ (2.5 eq), DCM (0.2 M), 85 °C, 24 h 18 examples, 21-82 % yield R ¹ : Me, OCH ₃ , COOMe, CF ₃ , F, COOMe R ² : Ph, PhMe, PhOMe, furane, thiophene, cyclohexanone	415
3		Alkenylation			Substrate (1 equiv), alkene (3 equiv), [Cp*RhCl ₂] ₂ (5 mol %), AgSbF ₆ (20 mol%), Cu(OAc) ₂ (2.1 equiv), and THF (0.1 M) in a sealed vial for 20 h at 75 °C 16 examples, 46-96 % yield R ¹ : Alkyl, aryl, COOEt R ² : <i>i</i> -Propyl, cyclohexanone, (alkyl)halogenide, Ph, COOEt, OAc, Bu	416
4		Amidation			Substrate (0.2 mmol), N-OTs phthalimide (0.3 mmol), [RhCp*Cl ₂] ₂ (5 mol%), AgSbF ₆ (40 mol%), DCE (2 mL), 100 °C, 20 h, sealed tube under argon 23 examples, 56-60 % R ¹ : Ph, OMe	417

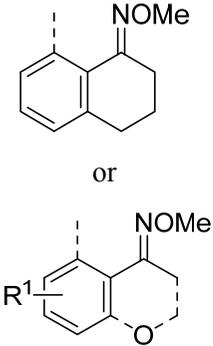
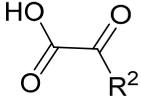
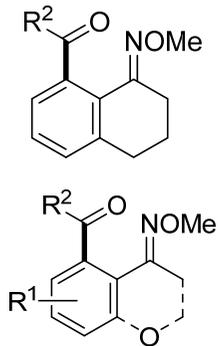
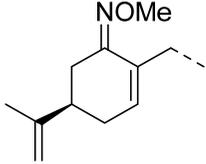
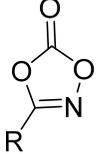
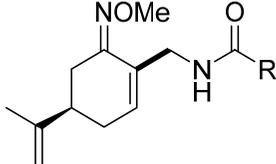
5					Substrate (0.2 mmol), coupling partner (0.22 mmol); large scale: substrate (50 mmol), [RhCp*Cl2]2 (0.5 mol%), AgNTf2 (2 mol%), ethyl acetate, 60 °C, 18 h 2 examples, 51-64 % recrystallization yield (Br) R ¹ : H, Br	418
6		Cyanation			Substrate (0.2 mmol), [RhCp*(CH3CN)3](SbF6)2 (5 mol %), and Ag2CO3 (20 mol%), dioxane, Ar, 24 h, heterocycles tolerated 25 examples, 53-94 % yield R ¹ : Me, halogenide, COOMe, OMe, OTs, NHAc, OH, alkoxy, sugar residues	212
7		Cyclization			Substrate (1 eq), alkyne (3 eq), [Cp*RhCl2]2 (2.5 mol%), 2 eq. Cu(OAc)2, 0.5 eq. NaOAc, MeOH, 110 °C, 2h, heterocycles tolerated 16 examples, 23-96 % yield R ¹ : OH, Me, OMe, NHAc, CF3	432
8		Diazo coupling			Substrate (0.4 mmol), diazomalonat (0.2 mmol), [Cp*RhCl2]2 (1.25 mol%), AgOAc (7.5 mol %), MeOH, 60 °C, 12 h 13 examples, 36-93 % yield R ¹ : OMe, CF3, SO2Me, CO2Et, Br	153
9		Allylation			Substrate (0.2 mmol, 1.0 equiv), vinyloxirane (1.2 equiv), [RhCp*Cl2]2 (3 mol%), AgSbF6 (12 mol%), THF (2 ml), 50 °C, 12 h, Cu(OAc)2 (0.5 equiv) 8 examples, 51-84 % yield R ¹ : Me, halogenide, NO2 R ² : Me, alkyl, (cyclic alkyl)	420

10		Amidation	Amide (H ₂ NCOR ³)		Substrate (1 eq), amide (1.2 eq), Pd(OAc) ₂ (5 mol%), K ₂ S ₂ O ₈ , DCE, 80 °C, 14-20 h 9 examples, 87-96 % yield R ¹ : Me, OMe, halogenide R ² : H, Me R ³ : CO ₂ CH ₃ , COCF ₃ , CO ² <i>t</i> Bu, SO ₂ CH ₃ , SO ₂ (<i>p</i> -Cl-C ₆ H ₄), COCH=CHC ₆ H ₄	421
11		Arylation			Substrate (0.2 mmol), boronic acid (0.5 eq every 2 hours)Pd(OAc) ₂ (10 mol%), Cu(OTf) ₂ (2 eq), O ₂ (1 atm), dioxane, 100 °C, 24 h 28 examples, 5-87 % yield R ¹ : Me; R ² : Me, alkyl (cyclized); R ³ : H, Me, <i>t</i> Bu, halogenide, OMe, OCF ₃ ; R ⁴ : Me, Bn, Ph, Ac, Bz, Piv	433
12		Arylation			Substrate (0.2 mmol), boronic acid (0.5 eq every 2 hours) One pot procedure, 1) Pd(OAc) ₂ (10 mol%), Cu(OTf) ₂ (2.5 eq), 3 A-MS, dioxane, 90 °C; 2) TfOH (2 eq); 3) HCl (6 M) 8 examples, 39-62 % yield R ¹ : Me; R ³ : Me, <i>t</i> Bu, OMe	433
13		Fluorination			Substrate (0.3 mmol), [Pd ₂ (dba) ₃] (5 mol%), NFSI (2.0 equiv), KNO ₃ (30 mol%), 3 ml CH ₃ NO ₂ , NFSI (N- fluorobenzenesulfonimide) 27 examples, 65-87 % yield R ¹ : Me, OMe, OBn, Ph, halogenide, COOMe, SO ₂ Me, CN, NO ₂ , CF ₃ , naphthyl; R ² : Alkyl, Ph	422

14		Heteroarylation			Substrate (0.25 mmol), 2-chlorothiophene (0.375 mmol), [Cp*RhCl ₂] ₂ (2.5 mol%), Ag ₂ CO ₃ (2.2 equiv.), Cu(TFA) ₂ , H ₂ O (20 mol%), DCE (0.6 mL) at 150 °C for 24 hours under an N ₂ atmosphere 29 examples, 44-70 % yield R ¹ : COOEt, NO ₂ ; R ² : Me; Ph	426
15		Hydroxylation	Oxone		Substrate (0.3 mmol), Pd(OAc) ₂ (5 mol%), PPh ₃ (10 mol%), KHSO ₅ , Oxone (1.2 equiv), CHCl ₂ CHCl ₂ (1 mL) was stirred at 100 °C for 24 h under air 43 examples, 32-98 % yield R ¹ : H, Me, Ph, naphthyl, OMe, <i>t</i> -Bu, F; R ² : Aryl, alkyl, cyclized alkyl, COH, CH ₂ CH ₂ COOCH ₃ , alkylhalogenide	423
16		Nitration	AgNO ₂		Substrate (0.3 mmol), Pd(OCOCF ₃) ₂ (10 mol%) (0.03 mmol), AgNO ₂ (2 eq) (0.6 mmol), K ₂ S ₂ O ₈ (2 eq) (0.6 mmol) in 3.5 mL of DCE at 110 °C for 48 h Bicycles (R ² -) potential substrates 23 examples, 42-90 % yield R ¹ : Me, OMe, halogenide, NO ₂ , SO ₂ Me, OBn R ² : Me, (cyclized) alkyl, Ph	424
17		Selenylation	PhSe-Cl PhSe-SePh		Substrate (0.2 mmol), coupling partner (0.24 mmol), [Cp*RhCl ₂] ₂ (4 mol%), AgSbF ₆ (1.5 equiv), NaOAc (1.2 equiv), THF (3 mL), 60 °C, 20 h, sealed tube under N ₂ . 29 examples, 45-94 % R ¹ : OMe, <i>t</i> Bu, COOMe, halogenide, alkyl, Ph, CF ₃	425

18		Amidation, Cyclization			Substrate (0.2 mmol), isocyanate (0.3 mmol), [Rh(CH ₃ CN) ₃ (Cp*)][SbF ₆] ₂ (5 mol%), DCE (1 mL), 100 °C, 12 h, oxime serves first as DG, then as leaving group 17 examples, 74-92 % yield R ¹ : CF ₃ , COOMe, OMe, halogenide; R ² : Me, alkyl, aryl R ³ : PhMe	434
19		Cyclization			Substrate (0.20 mmol), alkyne 2 (0.30 mmol) Cu-(OAc) ₂ ·H ₂ O (0.70 mmol) and [RhCp*Cl ₂] ₂ (0.004 mmol) in MeOH (0.2 M) under N ₂ . Route to <i>meta</i> and <i>ortho</i> substituted benzofurans 22 examples, 34-94 % yield R ¹ : OMe, halogenide ; R ² : H, Me, cyclyzed alkyl R ³ : Ph, PhMe, PhMeO, Ph-halogenide	427
20		Acetylation	PhI(OAc) ₂		Substrate (1 eq), 1.1 equiv of PhI(OAc) ₂ , 5 mol% Pd(OAc) ₂ , 50% AcOH/50% Ac ₂ O, 100 °C, 1.5-3.5 h. 13 examples, 39-68 % yield R ¹ : Alkyl R ² , R ³ : H, OAc	428
21		Arylation	Ar-I ⁺ OTf ⁻		Substrate (0.25 mmol), diaryliodonium salts (0.25 mmol), Pd(OAc) ₂ (5 mol%), PivOH (0.6 eq), Ag ₂ CO ₃ (2 eq), DCE:HFIP (3:1), 85 °C, 5 h 6 examples, 65-83 % yield R ¹ : H, Me, alkyl R ² : H, Me, COOEt	429

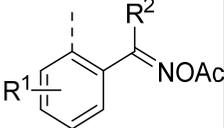
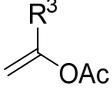
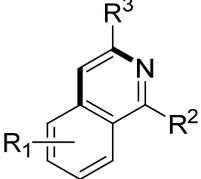
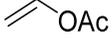
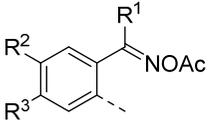
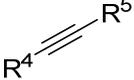
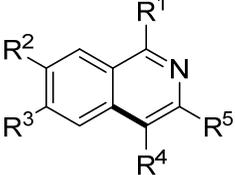
22		Amidation, Cyclization	$R^4-N=C=O$		Substrate (0.2 mmol), isocyanate (0.3 mmol), $[RhCp^*(CH_3CN)_3](SbF_6)_2$ (5 mol%), DCE, 100 °C, 12 h 19 examples, 47-93 % yield R^1 : H, Me; R^2 : H, Me; R^3 : Me, Ph, PhMe, PhMeO, Ph- halogenide, cyclized alkyl, naphthyl R^4 : PhMe, PhOMe, PhNO ₂ , PhCF ₃ , PhCOOEt, Ph- halogenide, naphthyl, alkyl, cyclohexane	435
23		Cyclization			Substrate (0.2 mmol), aldehyde (0.4 mmol) or imine (0.4 mmol), $[Cp^*RhCl_2]_2 / AgSbF_6$ (5 mol%), $AgBF_4$ (16 mol%), THF, 90 °C, 24 h 28 examples, 41-89 % yield R^1 : Me, alkyl; R^2 : Me, alkyl, Ph, tolyl; R^3 : H, Me R^4 : COOEt, PhMe, PhOMe, PhNO ₂ , PhCF ₃ , PhCOOEt, Ph- halogenide, naphthyl, alkyl, cyclohexane X= O, NTs	436
24		Cyclization	R^4-CHO		Co(III) conditions: Substrate (0.20 mmol), aldehyde (0.40 mmol), $[Cp^*CoCl_2]_2$ (10 mol%), and AcOH (10 mol%) in 1,4-dichloroethane (2.0 M) for 24 h 12 examples, 25-84 % yield Rh(III) conditions: Substrate(0.20 mmol), aldehyde (0.40mmol), $[Cp^*RhCl_2]_2$ (5/10 mol % of Rh dimer), and $AgSbF_6$ (20/ 40 mol %) in tetrahydrofuran (0.3 M) at 90 °C for 24 h 12 examples, 41-76 % yield R^1 : Ph, tolyl, cyclized alkyl; R^2 : Alkyl, Ph, Ph-halogenide, PhMe, PhCOOMe, PhCF ₃ ; R^4 : Aryl, alkyl	430

1		Acylation			Substrate (0.3 mmol), α -keto acid (0.45 mmol), Pd(OAc) ₂ (10 mol%), (NH ₄) ₂ S ₂ O ₈ (0.45 mmol), diglyme (1 mL), 70 °C in sealed tubes (3 h -10 h) 24 examples, 36- 85 % yield R ¹ : Halogenide, MeO, CF ₃ R ² (if R ¹ present): Ph R ² : Ph-halogenide, PhMeO, PhCF ₃ , naphthyl, thiophene	431
2		Amidation			Substrate (0.2 mmol), dioxazolone (0.21 mmol), AgOAc (8 mol%), [RhCp*Cl ₂] ₂ (4mol%), AgSbF ₆ (16 mol%), DCM (3.0 mL), 25 °C, 12 h, sealed tube under nitrogen. 11 examples, 21-86 % yield R: Ph, PhMe, Ph-halogenide, PhCF ₃ , Ph- <i>t</i> -Bu, thiophen, amide	419

Ketoxim esters

Ketoxim esters of various types have been frequently applied in the synthesis of heterocycles such as isoquinolines and pyridines and their oxidized derivatives. The dominant catalyst in this chemistry is [Cp*RhCl₂]₂. The Matsunaga group demonstrated a protocol for the synthesis of multisubstituted isoquinolines by site-selective C-H activation of various unsymmetrically substituted ketoxime esters with terminal and internal alkynes. Notably, this procedure is Cp*Co^{III} catalyzed and thereby another example for non precious metal catalysis in C-H activation (Table 18, Entry 3).⁴³⁷ With regard to exceptional metal catalysts in the field, it is important to mention the copper catalyzed coupling of ketoxime esters with sodium sulfinates for the synthesis of sulfone derivatives developed by Tang et al. (Table 18, Entry 4).⁴³⁸ As already mentioned, ketoxime esters are furthermore utilized for the synthesis of pyridines via C-H activation. In 2013 the Rovis group displays a rhodium catalyzed regioselective pyridine synthesis, starting from alkenes and α,β -unsaturated oxime esters. The use of an *O*-pivaloyl ketoxime ester is obligatory since the respective *O*-acetyl ketoxime ester leads to the formation isoxazole instead of the desired pyridine (Table 19, Entry 3).⁴³⁹

Table 18: KetoximEster

Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
1		Cyclization			Substrate (0.4 mmol), vinyl acetate (1.2 mmol), [Cp*RhCl ₂] ₂ (4 mol%), AgBF ₄ (16 mol%), MeOH (2 mL), 100 °C, 12 h 20 examples, 33-87 % yield R ¹ : Me, MeO, alkyl, Ph, Ph-halogenide, PhCF ₃ , PHNO ₂ , R ² : Me, alkyl, Ph R ³ : H, Me, Ph, PhMe, PhCl, thiophene	440
2		Cyclization			Substrate (0.4 mmol), vinyl acetate (1.2 mmol), [Cp*RhCl ₂] ₂ (4 mol%), AgOAc (16 mol%), MeOH (2 mL), 100 °C, 12 h 12 examples, 40-90 % yield R ¹ : Me, MeO, alkyl, Ph, Ph-halogenide, PhCF ₃ , PHNO ₂ , R ² : Me, alkyl, Ph	440
3		Cyclization			Substrate (0.15 mmol), alkyne (0.18 mmol), [Cp*Co(CO)I ₂] (10 mol%), AgSbF ₆ (20 mol%), and KOAc (20 mol%) in ClCH ₂ CH ₂ Cl, 80-120 °C, 24 h, internal and terminal alkynes tolerated 56 examples, 45-97 % yield R ¹ : Aryl, alkyl; R ² : Alkyl, aryl, halogenide; R ³ : Alkyl, aryl, halogenide, MeO, CF ₃ ; R ⁴ : H, aryl, alkyl, ferrocen, pentathrenyl, thienyl; R ⁵ : Aryl, alkyl	437

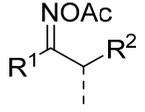
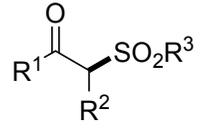
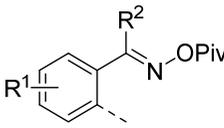
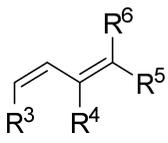
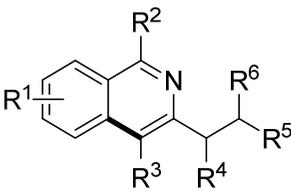
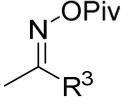
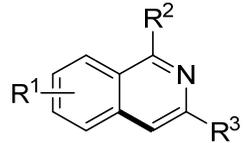
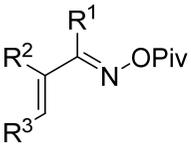
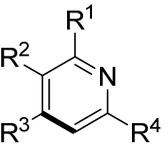
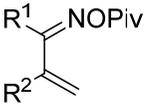
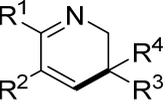
4		Sulfonylation	R^3SO_2Na		Substrate (0.5 mmol), sodium sulfinate (0.5 mmol), $Cu(OAc)_2$ (10 mol%), in toluene (2 mL) at 100 °C under N_2 stirring in DCM for 6 h, coupling with sodium sulfonates, subsequent hydrolysis; (removal of the DG) 30 examples, 70-96 % yield R^1 : Aryl, thiophene; R^2 : H; R^3 : Aryl, alkyl, naphthyl	438
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Table 19: Oxime Ester (Piv)

Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
1		Cyclization			Substrate (0.2 mmol), dienoate (0.25 mmol), $[Cp^*RhCl_2]_2$ (2.5 mol%), $AgSbF_6$ (15 mol%), PivOH (3.0 equiv.), aromatic o-pivaloylketoxime (0.2 mmol), and (E)-ethyl penta-2,4-dienoate (0.25 mmol) in DCE (1 mL) for 20 h at 100 °C under argon 27 examples, 44-91 % yield R^1 : Me, MeO, CF_3 , halogenide, NO_2 , CN; R^2 : Alkyl; R^3 : H, alkyl; R^4 : H $R^{5/6}$: ester, cyanide, aryl, alkyl, ketone, SOOPh, PO(OEt) ₂	441
2		Cyclization			Substrate (0.125 mmol), aryloxime pivalate (0.375 mmol), 0.05 mmol of $Pd(OAc)_2$, 6 mL of toluene in a sealed tube at 150 °C for 24/48h; selfcoupling (2 eq. oxime ester) 34 examples, 20-88 % yield R^1 : Me, MeO, ester, CF_3 , halogenide; R^2 : alkyl, aryl R^3 : aryl, vinyl, alkoxy carbonyl	442

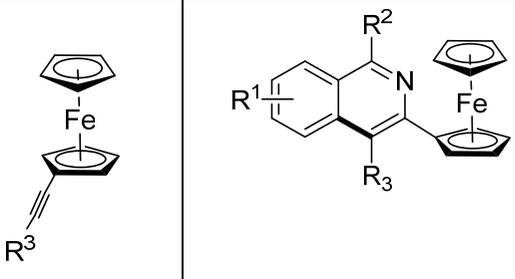
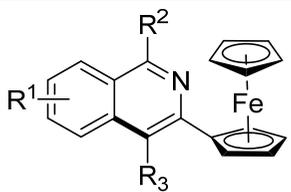
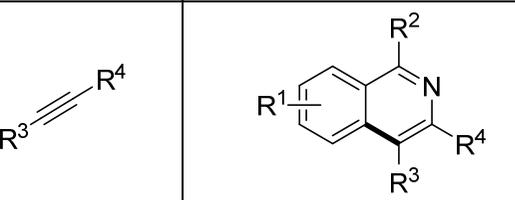
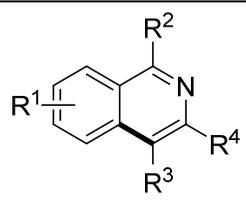
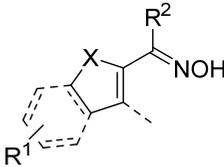
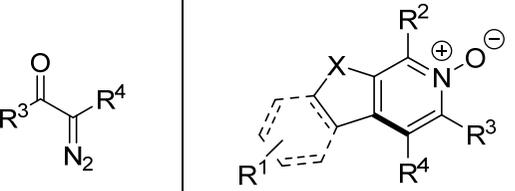
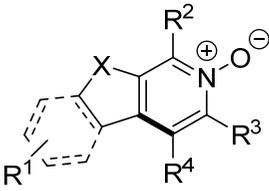
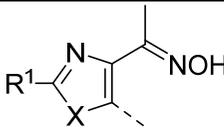
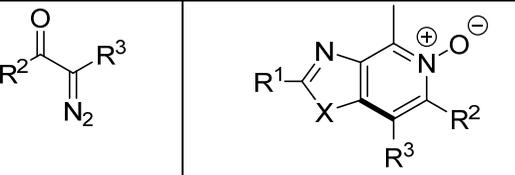
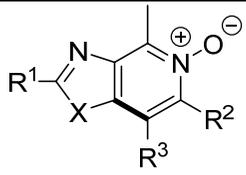
3		Cyclization			Substrate (0.21 mmol), alkene (0.25 mmol)[RhCp*Cl ₂] ₂ (0.005 mmol), and AgOAc (0.44 mmol) in 0.7 mL of 2:1 DCE/AcOH for 14 h. 26 examples, 33-96 % yield R ¹ : alkyl; R ² : alkyl, aryl; R ³ : H, alkyl R ⁴ : COOEt, Ph, Ph-halogenide, ketone, ester, amide	439
4		Cyclization			Substrate (1 eq), alkene (1.2 eq), Rh (III) catalyst, (cationic tris(acetonitrile) Rh(III) pre-catalyst bearing a trifluoromethyl-substituted Cp* ligand) [RhCpCF ₃ *(CH ₃ CN) ₃](SbF ₆) ₂ (2 mol %), CsOAc (2 eq.), HFIP, 50 °C 31 examples, 67- 88 % yield R ¹ : alkyl; R ² : alkyl, aryl; R ³ : alkyl; R ⁴ : alkyl, ester	443

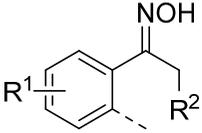
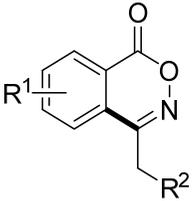
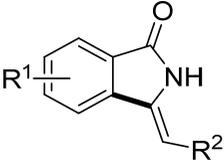
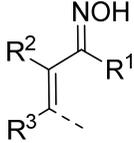
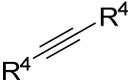
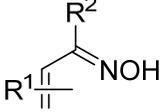
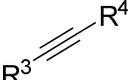
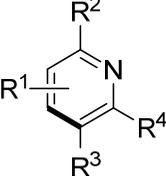
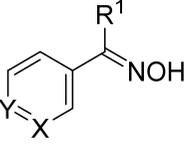
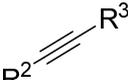
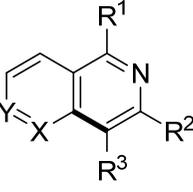
Ketoxime

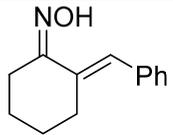
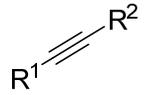
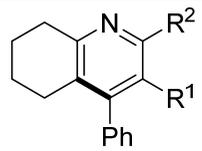
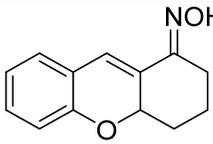
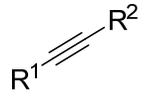
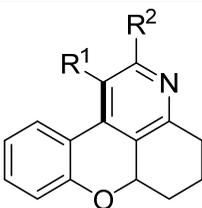
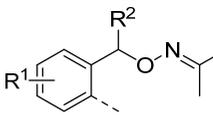
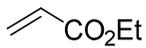
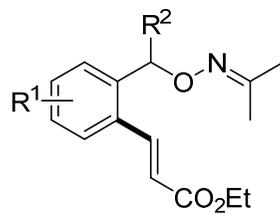
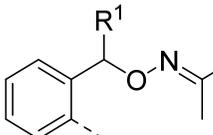
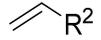
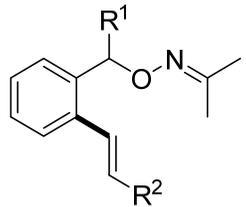
Concerning the ketoxime scaffold as directing group, again rhodium catalyzed processes are dominant. One was published in 2009 by Parthasarathy et al. The procedure describes a highly regioselective synthesis of isoquinoline derivatives from ketoximes and alkynes (Table 20, Entry 1).⁴⁴⁴ Thus, a cobalt(III) catalyzed protocol for the production of isoquinolins was demonstrated by Sen et al. In this case even oxime containing heterocycles are tolerated (Table 20, Entry 2).⁴⁴⁵ Moreover, the Glorius group developed a synthesis of multisubstituted isoquinolines and pyridine *N*-oxides via aryl and vinylic C-H activation (Table 20, Entry 4).⁴⁴⁶ Ketoximes can be used as directing groups in the desymmetrization of diazabicycles and thereby provide access to functionalized cyclopentenes (Table 20, Entry 3).⁴⁴⁷ The Ackermann group reported the first annulation of redox-active ferrocenylalkynes via catalyzed direct C-H/N-O bond functionalization using a ketoxime as directing group (Table 20, Entry 5).⁴⁴⁸ The Jiang group found that the N-OH group of the oximes could serve as a directing group and/or an internal oxidant under different conditions. They demonstrated a palladium catalyzed C(sp²)-H carbonylation of aromatic oximes and thus the access to benzooxazinones and 3-methyleneisoindolin-1-ones (Table 20, Entry 9).⁴⁴⁹ Further, a palladium catalyzed direct *ortho* functionalization of aromatic alcohols masked by acetone oxime ethers was developed. Guo et al. achieved as first group a selective alkenylation of aromatic alcohols via a six- or seven-membered *exo*-acetone oxime ether palladacycle (Table 20, Entry 16 & 17).⁴⁵⁰ In contrast, a rhodium catalyst would not serve the purpose in this mechanism.

Table 20: Ketoxime- based directing groups

Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
1		Cyclization			Substrate (1 mmol), alkyne (1.1 mmol), Rh(PPh ₃) ₃ Cl (3 mol%), 130 °C, toluene, 12 h, heterocycles tolerated 18 examples, 45-89 % R ¹ , R ² : H, alkyl, aryl	444
2					Substrate (0.2 mmol), alkyne (0.24 mmol), [Cp*Co(CO)I ₂] 10 mol%, NaOAc 20 mol%, CF ₃ CH ₂ OH, heterocycles tolerated 42 examples, 11- 90 % yield R ¹ : Aryl, alkyl R ² : Aryl, alkyl	445
3		Desymmetrization			Substrate (0.2 mmol), diazabicyclic (0.22 eq), [Cp*RhCl ₂] ₂ (2 mol %), AgOAc (8 mol%), MeOH (1.5 mL), 60 °C, 6 h, heterocycles tolerated 23 examples, 73-95 % yield R ¹ : Alkyl, aryl, OH, ketone, halogenide, NO ₂ , AcHN E: CO ₂ Et, CO ₂ tBu	447
4		Cyclization			Substrate (0.2 mmol), diazo compound (0.24 mmol), [Cp*RhCl ₂] ₂ (2.5 mol%), AgSbF ₆ (10.0 mol %), MeOH (1.0 mL), 60°C, 12 h, under Ar 25 examples, 45-99 % yield R ¹ : H, alkyl; R ² : Halogenide, OMe; R ³ : H, alkyl, aryl	446

					R ⁴ : Ester, aryl, PO(OMe) ₂ , SO ₂ PhMe, ketone	
5		Cyclization			Substrate (0.5 mmol), alkyne (1 mmol), [RuCl ₂ (<i>p</i> -cymene)] ₂ (5 mol%), MeOH, 80 °C, 24 h 13 examples, 55-95 % yield R ¹ : Alkyl, OMe R ² : Alkyl R ³ : Alkyl	448
6					Substrate (1.0 mmol), alkyne (1.3 mmol), [RhCp*Cl ₂ (1 mmol%), CsOAc (30 mmol%), methanol (4 mL), 60 °C, 12 h 15 examples, 20-95 % yield R ¹ : Halogenide, Me, MeO, naphthyl R ² : H, Me, Ph; R ³ , R ⁴ : Alkyl, aryl, MeOH	451
7		Cyclization			Substrate (0.5 mmol), diazo compound (1 mmol), (Cp*RhCl ₂) ₂ (2.5 mol%), NaOAc (2 eq), MeOH (2.0 mL) at 80 °C for 12 h under air atmosphere. 27 examples, 77-98 % yield X: O, S, N R ¹ : Alkyl, OMe, aryl, halogenide; R ² : Alkyl, aryl R ³ : H, Me, cyclized alkyl; R ⁴ : Ester, ketone	452
8		Cyclization			Substrate (0.5 mmol), diazo compound (1 mmol), (Cp*RhCl ₂) ₂ (2.5 mol%), NaOAc (2 eq), MeOH (2.0 mL) at 70 °C for 12 h under air atmosphere. 15 examples, 50-98 % yield X: O, S; R ¹ : Aryl; R ² : H, alkyl; R ³ : Ester	452

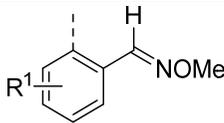
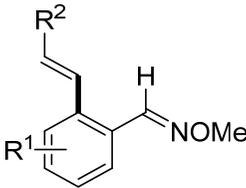
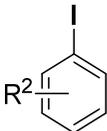
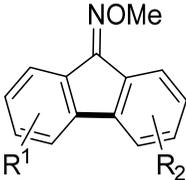
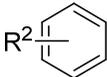
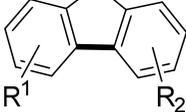
9		Carbonylation	CO		Substrate (0.5mmol), PdCl ₂ (0.05mmol), AgOAc (1.0 mmol), CO (balloon), C ₃ H ₇ COOH/(C ₃ H ₇ CO) ₂ O(2 mL, v/v= 20: 1), 100 °C 22 examples, 46-89 % yield R ¹ : alkyl, CF ₃ , OMe, condensed (hetero)cycles R ² : H, alkyl	449
10					Substrate (0.5 mmol), PdCl ₂ (0.05 mmol), K ₂ CO ₃ (0.25 mmol), CO balloon, n-C ₃ H ₇ COOH (2 mL), 120 °C 12 examples, 62-89 % yield R ¹ : Alkyl, OMe, TsO, F, CF ₃ ; R ² : Alkyl	449
11		Cyclization			Substrate (1 mmol), alkyne (1.1 mmol), Rh(PPh ₃) ₃ Cl (3 mol%), and toluene 130 °C, 3h 12 examples, 51- 94 % yield R ¹ : H, alkyl; R ² : Aryl, alkyl, thiophene R ³ : H, alkyl, thiophene, aryl; R ⁴ : Aryl, alkyl	453
12		Cyclization			Substrate, (0.2 mmol), alkyne (0.22 mmol), [Cp [*] RhCl ₂] ₂ (1.25 mol %) (or [Cp ^t RhCl ₂] ₂) K ₂ CO ₃ (0.4 mmol) in TFE, 45 °C, 16 h 26 examples, 45- 95 %yield R ¹ : Aryl, alkyl, CF ₃ , amide; R ² : H, alkyl R ³ : Alkyl, aryl, ester, CH ₂ OTBS; R ⁴ : Alkyl, (hetero)aryl	454
13		Cyclization			Substrate (0.2 mmol), alkyne (0.22 mmol), [Cp [*] RhCl ₂] ₂ (1.25 mol %) (or [Cp ^t RhCl ₂] ₂) K ₂ CO ₃ (0.4 mmol) in TFE, 45 °C, 16 h 13 examples, 70- 96 %yield X/Y: C, S, N, O	454

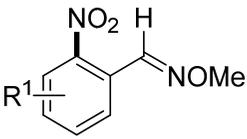
					<p>R¹: Aryl, alkyl R²: Ph R³: Alkyl</p>	
14		Cyclization			<p>Substrate (1 mmol), alkyne (1.1 mmol), Rh(PPh₃)₃Cl (3 mol%), 130 °C, toluene, 12 h 3 examples, 41-83 % yield R¹, R²: H, alkyl, aryl</p>	444
15		Cyclization			<p>Substrate (1 mmol), alkyne (1.1 mmol), Rh(PPh₃)₃Cl (3 mol%), 130 °C, toluene, 12 h 3 examples, 70-76 % yield R¹, R²: Alkyl</p>	444
16		Alkenylation			<p>Substrate (0.2 mmol), alkene (0.3 mmol), Pd(OAc)₂ (5 mol%), Ac-Val-OH (10 mol%), AgOAc (0.5 mmol), 1,4-dioxane (1 mL), 90 °C, 12 h 31 examples, 15 -95 % yield R¹: Alkyl, MeS, MeO, halogenide, NO₂ R²: H, alkyl</p>	450
17		Alkenylation			<p>Substrate (0.2 mmol), alkene (0.3 mmol), Pd(OAc)₂ (5 mol%), Ac-Val-OH (10 mol %), AgOAc (0.5 mmol), 1,4-dioxane (1 mL), 90 °C, 12 h 40 examples, 50 -77 % yield R¹: Alkyl R²: H, alcohol, carbonyl, SO₂Ph</p>	450

Aldoximes and aldoxime ether

In the case of aldoximes only few examples have been reported. The lower stability of the substrates is for sure an important reason for this fact. Still, arylation, alkenylations and even nitration has been reported. Typically, an acidic medium is required since basic conditions would lead to quick hydrolysis of the aldoxime DG, especially at the high temperatures usually required for C-H activation.

Table 21: Aldoxime- based directing groups

Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
1		Alkenylation			Substrate (0.5 mmol), alkene (1.0 mmol), BQ (0.5 mmol), Pd(OAc) ₂ (2.24 mg, 0.01 mmol, 2 mol%), and acetic acid (2 mL) were added in a 25 mL sealed tube with a teflon lined cap. The mixture was heated at 80 °C for 6 h. 21 examples, 51-93 % yield R ¹ : Alkyl, halogenide, OMe, OH R ² : Ester	455
2		Arylation			Substrate (1.0 mmol), aryl iodide 2 (5-6 equiv), Pd(OAc) ₂ (1.0 mmol) and CF ₃ CO ₂ H (10 mol%), Ag ₂ O (2.0 mL), 120 °C, 36 h 18 examples, 63-90 % yield R ¹ : Me, halogenide R ² : Me, NO ₂ , ester, OMe	456
3					Substrate (80.7 mmol), arene (2 ml), Pd(OAc) ₂ (20 mol %), K ₂ S ₂ O ₈ (1.4 mmol), TFA (7.0 mmol), 120 °C, 15h 22 examples, 51-91 % yield R ¹ : Me, halogenide R ² : Me, NO ₂ , ester, OMe	457

4		Nitration	AgNO ₂		Substrate (0.3 mmol), Pd(OCOCF ₃) ₂ (0.03 mmol), AgNO ₂ (0.6 mmol), K ₂ S ₂ O ₈ (0.6 mmol), DCE (3.0 mL), 110 °C, 48 h 24 examples, 38- 93 % yield R ¹ : Halogenide, CF ₃ , alkyl, aryl, OMe, naphthyl	458
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Phosphorous-containing directing groups

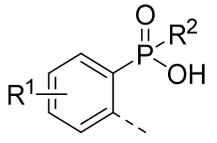
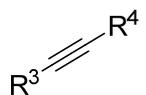
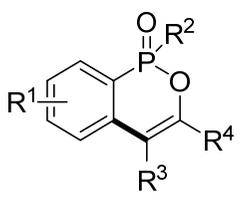
P-containing directing groups have been added relatively late to the toolbox of C-H activation chemistry. Typically, it is not P-which coordinates to a metal catalyst, but a heteroatom attached to it, most importantly oxygen and to a lesser extent nitrogen. Within the last three years, a series of examples have been disclosed, which demonstrate the high synthetic potential of P-containing functional groups as directing groups in C-H activation chemistry. Phosphinic acid, phosphonic acids, and phosphoric acids as well as the respective ester derivatives have been used so far. Additionally, simple phosphine oxides, phosphoramides, phosphoramidic acids and phosphinic amides have been applied.

Several examples have been disclosed in which the directing group is additionally reacting with a coupling partner in cyclization reactions to give mainly oxaphosphanes or oxaphospholanes and to a lesser extent azaphosphanes and azaphospholidines as well as phosphoindoles. The main contributor in this field of cyclizations towards P-containing heterocycles was the group of Lee. They demonstrated the application of phosphorus containing directing groups for the synthesis of phosphorous heterocycles under aerobic conditions under ruthenium and rhodium catalysis in an intermolecular fashion using either alkynes or alkenes as coupling partners.⁴⁵⁹⁻⁴⁶² Additionally, they reported intramolecular cyclization reactions. Interestingly, in these cases, simple Pd(OAc)₂ could be applied as the catalyst.^{463, 464} The required oxidant for these transformations had to be optimized for each individual case.

The Han group was the first, who employed a phenylphosphinic acid in the sense of a directing group in C-H activation. A new oxapalladacycle was conveniently prepared via direct *ortho* palladation of diphenylphosphinic acid with palladium acetate.⁴⁶⁵ In 2014 Zhang et al. demonstrated a novel and efficient Pd-catalyzed C-H acetoxylation, which uses R₂(O)P as a directing group to synthesize various substituted phosphorylbiphenyl-2-OAc compounds (Table 22, Entry 18).⁴⁶⁶ The Kim group has focused on the application of organophosphates as directing group in C-H activation. For instance, a palladium(II) catalyzed *ortho*-arylation of aryl phosphates and aryl hydrogen phosphates were demonstrated in 2013 (Table 23, Entry 4).⁴⁶⁷ Further, a procedure for Pd-catalyzed acetoxylation of benzyl phosphonic and aryl phosphoric monoacids, providing access to various acetoxy benzylic phosphonic acids along with catechol derivatives (Table 22, Entry 12).⁴⁶⁸ In contrast to that, the Duan group demonstrated an Ag-mediated C-H/P-H functionalization of arylphosphine oxides with internal alkynes (Table 23, Entry 9).⁴⁶⁹ Chary et al. described first phosphoramidate directing group for synthetically useful arylation. This new directing group drives selective C-H bond activation to afford *N*-aryl phosphoramidates in good to excellent yields at room temperature (Table 22, Entry 5).⁴⁷⁰ The synthesis of another nitrogen containing scaffold by application of phosphorus containing directing groups was demonstrated by Park et al. The rhodium-

catalyzed oxidative coupling via C–H activation and annulation directed by phosphonamide and phosphinamide group functions under aerobic conditions and yields benzazaphosphole 1-oxides and phosphaisoquinolin-1-oxides (Table 23, Entry 7).⁴⁷¹ Itoh et al. described a ruthenium catalyzed process: a wide range of tri-, di-, and monoarylphosphine oxides efficiently undergo *ortho*-alkenylation through insertion of alkynes, which is environmentally benign because no oxidant such as stoichiometric silver or copper salts is needed (Table 22, Entry 17).⁴⁷² The Lee group demonstrated the application of phosphorus-containing directing groups for the synthesis of phosphorous heterocycles under aerobic conditions under ruthenium and rhodium catalysis (Table 23, Entry 7) and (Table 22, Entry 1&2).^{459, 460, 471} The access to diverse P-containing functional frameworks via rhodium(III)-catalyzed oxidative C-H activation of arylphosphonates and phosphonamides with subsequent coupling with alkenes (olefination), internal alkynes (hydroarylation and oxidative cyclization), or arenes was reported by the Glorius group (Table 22, Entry 13).⁴⁷³

Table 22: Phosphonic acid and derivatives as directing groups

Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
1		Cyclization			Substrate (0.2 mmol), alkyne (0.3 mmol), [RuCl ₂ (<i>p</i> -cymene)] ₂ (10 mol%), the most common oxidant Cu(OAc) ₂ ·H ₂ O for oxidative alkyne annulation reactions was found to be ineffective, and a mixture of silver salts was required as the sacrificial oxidants; KPF ₆ (20 mol %); AgCO ₃ (1 eq.); AgOAc (1 eq.); <i>t</i> -BuOH; 90°C; under air 34 examples, 27- 97 % yield R ¹ : H, alkyl, halogenide, ether, carbonyl, AcMeO, OH, (OCH ₂ O) naphthalenyl, indenyl, thiophenyl, OMe R ² : OEt, Ar; R ³ , R ⁴ : Alkyl, aryl	⁴⁶⁰
2					Substrate (0.15 mmol), alkyne (0.23 mmol), [Cp*RhCl ₂] ₂ (2 mol%); Ag ₂ CO ₃ (0.15 mmol), AgOAc (0.15 mmol), <i>t</i> BuOH (1 mL), 90 °C, under air 44 examples, 60-95 % yield R ¹ : Alkyl, halogenide, ether, carbonyl, AcMeO, OH,	^{459, 461}

					(OCH ₂ O) naphthalenyl, indenyl, thiophenyl, OMe R ² : OEt, Ar; R ³ , R ⁴ : Alkyl, aryl	
3		Arylation	Ar ₂ IOTf		Substrate (0.15 mmol), Pd(TFA) ₂ (10 mol%); Ph ₂ IOTf (2 eq.); 1,2-dichloroethane; 80°C; 15 h 12 examples, 29-75 % yield R ¹ : Alkyl, halogenide, OMe R ² : H, Me, CH ₂ C(CH ₃) ₂ CH ₂ , OH; R ³ : Me	467 474
4		Cyclization	Intramolecular		Substrate (0.2 mmol), Pd(OAc) ₂ (10 mol%); (4-MeO-C ₆ H ₄) ₃ P (0.4 eq.); Ag ₂ CO ₃ (3 eq.); K ₂ HPO ₄ (2.5 eq.); PhCl ; 120°C, 12-36 h; phosphinic acid with methylgroup in ortho position 16 examples, 43-81 % yield R ¹ : H, Alkyl, aryl , OMe, OPh, halogenide, CF ₃ , TMS R ² : Alkyl R ³ : OMe, OEt, Me, Ph	463
5		Cyclization	Intramolecular		Substrate (0.2 mmol), Pd(OAc) ₂ (10 mol%), PhI(OAc) ₂ (0.3 mmol), NaOAc (0.2 mmol), 80 °C, 20 h, DCE (2 mL) 20 examples, 55-76 % yield R ¹ : Alkyl, aryl , OMe, halogenide, CF ₃	463
6		Cyclization	Intramolecular		Substrate (1 eq), PhI(OAc) ₂ (2.0 equiv.), Pd(OAc) ₂ (10mol%), KOAc (2 equiv.), <i>t</i> BuOH, 30 mol% <i>N</i> -acetyl-L-Leucin, 12 h, air atmosphere, 100 °C 20 examples, 50-72 % yield R ¹ , R ² : Me, OMe, halogenide, naphthyl	464

7		Cyclization			Substrate (0.2 mmol), alkene (2 eq), [Cp*RhCl2]2 (4 mol%); AgOAc (2 eq.), Na2HPO4 (1 eq.), and CH3CN; 110°C; 16 h 16 examples, 61-90 % yield R ¹ : Me R ² : CO-alkyl, CN, CONMe ₂ , SO ₂ PH, PO(OMe) ₂	462
8		Cyclization			Substrate (0.2 mmol), alkene (2 eq), [Cp*RhCl2]2 (4 mol%); AgOAc (2 eq.), Na2HPO4 (1 eq.), and CH3CN; 110°C; 24 h 8 examples, 59-76 % yield R ¹ : Alkyl, aryl, halogenide, OMe, OAc	
9		Cyclization			Substrate (0.15 mmol), alkyne (0.15 mmol), [(Cp*RhCl2)2] (2 mol%), Ag2CO3 (1 equiv), DMF (1 mL), 120 °C, 10 h under N ₂ . 11 examples, 75-91 % yield R ¹ , R ² , R ³ : Aryl, alkyl	459
10		Alkenylation			Substrate (1 eq), alkene (2 eq), 1.) Pd(OAc) ₂ (10 mol%), AgOAc (3 equiv.), dioxane, 110 °C, 24 h 2.) TMS-CHN ₂ , CH ₃ OH, 0.5 h, rt 27 examples, 55-96 % yield R ¹ : OMe, OH R ² : CO ₂ Et, aryl, alkyl, carbonyl, ester	475
11		Arylation	ArBF ₃ K		Substrate (1 eq), PhBF ₃ K (3 eq), PdCl ₂ (PET ₃) ₂ (10 mol %), Ac -Val-OH (20 mol%), Ag ₂ O (2 equiv), and KHF ₂ (1 equiv) in <i>t</i> -BuOH at 110 °C for 24 h 27 examples, 18-95 % yield	476

					R^1 : Alkyl, naphthyl, CF_3 , halogenide, OMe	
12		Acetoxylation	$PhI(OAc)_2$		Substrate (0.15 mmol), 1.) 2-3 equiv of $PhI(OAc)_2$, 5 mol% $Pd(OAc)_2$ in 1 mL of 1,2-dichloroethane for 15 h at 110 °C. 2.) 5 equiv of $TMSCHN_2$ in 0.5 mL of MeOH at rt for 30 min 27 examples, 53-95 % yield X: CH_2 , O R^1 : Alkyl, halogenide, OMe, CF_3	468
13		Arylation			Substrate (1 eq), arene (40 eq), 2.5 mol% $[RhCp^*Cl_2]_2$, 10 mol% $AgSbF_6$, 2.2 eq $Cu(OAc)_2$, 1 eq PivOH, 20 mol% $CsOPiv$, 160 °C, 24h 1 example, 41 % yield	473
14		Cyclization			$RhCp^*(CH_3CN)_3(SbF_6)_2$, 2 eq $Cu(OAc)_2$, DCE, 130 °C, 24 h 5 examples, 71-77 % yield R^1 : H R^2 : OEt, NEt_2 , $NHPr$ R^3, R^4 : aryl, alkyl	
15		Heck reaction			$RhCp^*(CH_3CN)_3(SbF_6)_2$, $Cu(OAc)_2$, DCE, under air, 130 °C, 24 h 9 examples, 77-94 % yield R^1 : Me, halogenide, OMe, naphthyl; R^2 : OEt, NEt_2 R^3 : O^tBu , OEt	

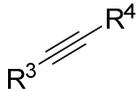
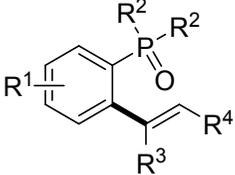
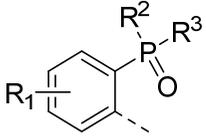
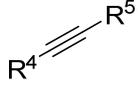
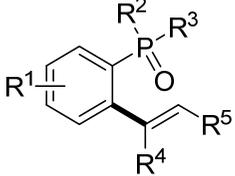
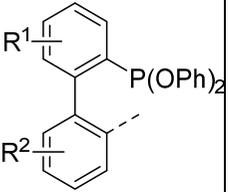
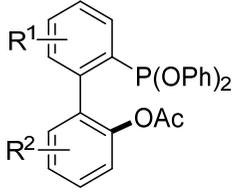
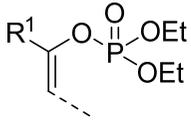
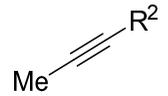
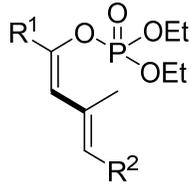
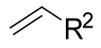
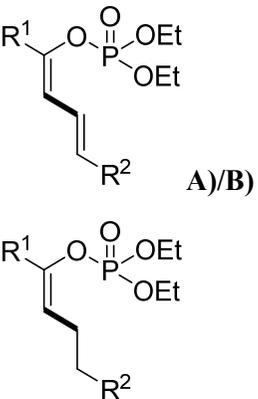
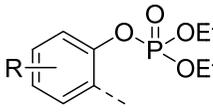
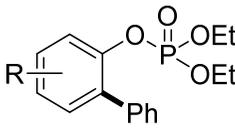
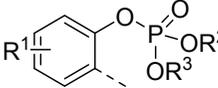
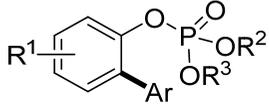
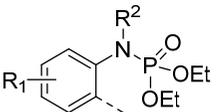
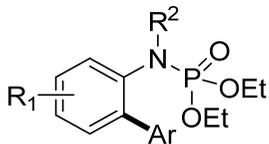
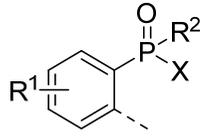
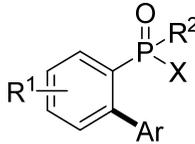
16		Hydroarylation			2.5 mol% [RhCp*Cl ₂] ₂ , 10 mol % AgSbF ₆ , 10 mol % Cu(OAc) ₂ , 1 eq. PivOH, DCE, 110 °C, 24 h 6 examples, 72-83 % yield R ¹ : Me, naphthyl; R ² : OEt, NEt ₂ ; R ³ , R ⁴ : Aryl	
17		Alkenylation			Substrate (1.25 mmol), alkyne (0.25 mmol), [RuCl ₂ (<i>p</i> -cymene)] ₂ (5 mol%); AgSbF ₆ (20 mol%); AcOH (4 eq.), dioxane; 100 °C; substituted styrene derivatives were obtained in a regio- and stereoselective fashion upon treatment of tri-, di-, or monoarylphosphine oxides with internal alkynes. 22 examples, 20-98 % yield R ¹ : Me, OMe, halogenide; R ² , R ³ ,: Aryl R ⁴ , R ⁵ : Aryl, alkyl, thiophenyl	472
18		Acetoxylation	PhI(OAc) ₂		Substrate (0.2 mmol), PhI(OAc) ₂ (3.0 equiv.), Pd(OAc) ₂ (10mol%), CF ₃ CH ₂ OH (2.0mL), air atmosphere, 100 °C 20 examples, 25-79 % yield R ¹ : Me, CF ₃ ; R ² , R ³ : Me, OAc, ester, halogenide	466

Table 23: Phosphates and derivatives as directing groups

Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
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1		Alkenylation			<p>Substrate (0.15 mmol), alkyne (0.15 mmol), [(Cp*<i>RhCl</i>₂)₂] (2.5 mol%), AgSbF₆ (10 mol%) and Cu(OAc)₂·H₂O (20 mol %), PivOH (1.1 equiv.), in THF at 40 °C for 17 h.</p> <p>5 examples, 34-83 % yield</p> <p>R¹: Aryl</p> <p>R²: Aryl, ester, ketone</p>	477
2		<p>A) Alkenylation B) Hydroalkenylation</p>		 <p style="text-align: center;">A)/B)</p>	<p>A) Substrate (0.15 mmol), alkene (2 eq), [(Cp*<i>RhCl</i>₂)₂] (2.5 mol%), AgSbF₆ (10 mol%) and Cu(OAc)₂·H₂O (1.1 equiv.), in THF at 80 °C for 17 h.</p> <p>41 examples, 20-90 % yield</p> <p>B) Substrate (0.15 mmol), enone (2 eq), [(Cp*<i>RhCl</i>₂)₂] (2.5 mol%), AgSbF₆ (10 mol%) and Cu(OAc)₂·H₂O (60 mol %), in THF at 80 °C for 17 h.</p> <p>10 examples, 35-89 % yield</p> <p>R¹: Aryl</p> <p>R²: A) CO₂R (ester), B) COR (ketone)</p>	
3		Arylation	PhI(OAc) ₂		<p>Substrate (0.25 mmol), diphenyliodonium triflate (0.5 mmol), Pd(OTf)₂·2 H₂O (0.025 mmol), and Na₂CO₃ (0.25 mmol) in 1,2-dichloroethane (1.0 mL, 0.25 M) at the designated temperature under Ar for 1 h.</p> <p>20 examples, 27-91 % yield</p> <p>R: OMe, alkyl, halogenide</p>	474

4		Arylation	Ar_2IOTf		Substrate (0.15 mmol), $\text{Pd}(\text{TFA})_2$ (10 mol%); Ph_2IOTf (2 eq.); 1,2-dichloroethane; 80°C; 15 h 12 examples, 29-75 % yield R^1 : Alkyl, halogenide, OMe R^2 : H, Me, $\text{CH}_2\text{C}(\text{CH}_3)_2\text{CH}_2$, OH R^3 : Me	467 474
5		Arylation	R^3_2IOTf		Substrate (0.3 mmol), $\text{Pd}(\text{OAc})_2$ (5 mol%); Ar_2IOTf (1.2 eq.), TfOH, (20 mol %); CuO (3 eq.); 1,4-dioxane; 25 °C 24 examples, 68-83 % yield R^1 : Me, Et, <i>tert</i> Bu, Bn, MeO, EtO, PhO, halogenide R^2 : H, Me, Et, <i>n</i> Bu R^3 : Aryl	470
6		Arylation	$\text{ArB}(\text{OH})_2$		Substrate (0.25 mmol), boronic acid (0.5 mmol) $\text{Pd}(\text{OAc})_2$ (10mol%), BQ (10mol%); CsF (1 eq.); AgCO_3 (1.5 eq); DMF; 40°C; 12h; under nitrogen; mixture of mono- and di-orthoarylated product. (BQ plays a critical role in the transmetalation or reductive elimination step. Previous reports have suggested that BQ could improve the reaction through promoting the reductive elimination in C-H activation/C-C bond formations). 27 examples, 16-64 % yield X: NHC_6F_5 , OMe, NEt_2 , NHC_3H_7 , $\text{N}(\text{OMe})\text{Me}$ R^1 : Alkyl, halogenide R^2 : Aryl	478

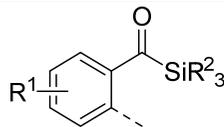
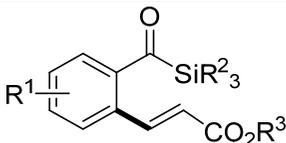
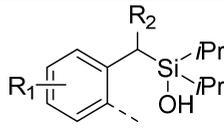
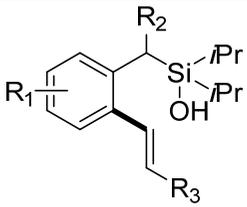
7		Cyclization			Substrate (0.2 mmol), alkene (0.4 mmol), [Cp*RhCl2]2 (4 mol%), TEMPO (0.5 mmol), CsOPiv (0.15 mmol), xylene (0.8 mL) at 110 °C for 20 h. 20 examples, 55-98 % yield R ¹ : Me, OMe, halogenide, CF ₃ , Ac, NO ₂ R ² : OEt R ³ : Ester, CN, SO ₂ Ph	471
8		Cyclization			Substrate (0.15 mmol), alkyne (0.3 mmol), [Cp*RhCl2]2 (4 mol%), AgCO ₃ (0.3 mmol), KH ₂ PO ₄ (0.15 mmol), <i>t</i> BuOH, 110 °C for 16 h. 16 examples, 60-99 % yield R ¹ : Me, OMe, halogenide, CF ₃ R ² : Aryl R ³ : Alkyl, aryl	
9		Cyclization			Substrate (2 eq), alkyne (1 eq), Ag ₂ O (5 mol% or 2 equiv.), Zn(NO ₃) ₂ ·6H ₂ O (1 equiv.), DMF, 100 °C, 12 h 17 examples, 22-94 % yield R ¹ : Me, OMe, halogenide R ² : Aryl R ³ , R ⁴ : Alkyl, aryl	469

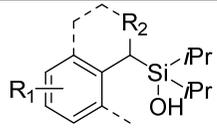
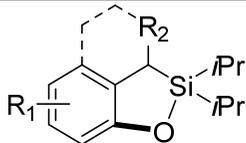
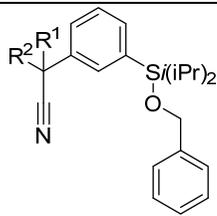
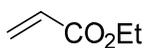
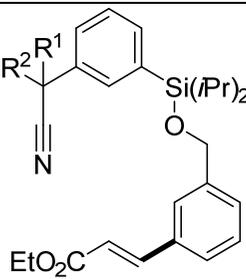
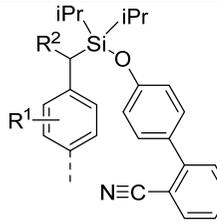
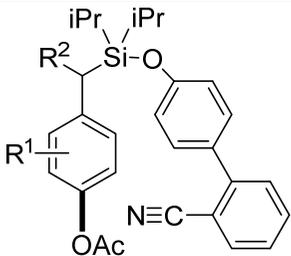
Si-containing directing groups

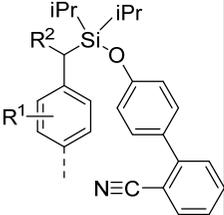
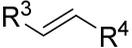
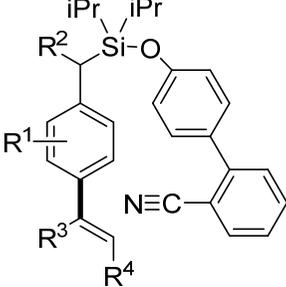
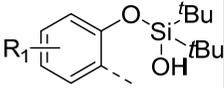
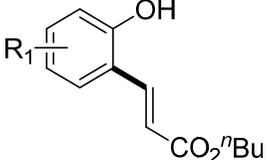
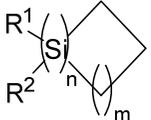
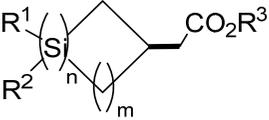
Hatanaka et al. demonstrated in 1997 a general approach for the synthesis of functionalized silacycloalkanes, via Rh-catalyzed carbenoid insertion into the β -C-H bonds of silacycloalkanes (Table 24, Entry 8).⁴⁷⁹

Further, acylsilanes were employed by Becker et al. in a rhodium-catalyzed olefination process for *ortho* olefinations of arylsilanes (Table 24, Entry 1).⁴⁸⁰ Another palladium catalyzed alkenylation procedure of arenes using silanol as directing group was described by Wang et al. in 2011 (Table 24, Entry 2).⁴⁸¹ A cyclization procedure was reported by the Gevorgyan group. In this protocol a Pd-catalyzed benzylsilanol directed *ortho* C-H oxygenation of aromatic rings and further the applicability of silanol as a traceless directing group for Pd-catalyzed *o*-alkenylation of phenols was demonstrated (Table 24, Entry 3).⁴⁸² Furthermore an efficient Pd-catalyzed *meta*-directing group based on a silicon tether was developed by Lee et al. The C-H activation was successful for different substitution patterns on the aromatic ring, and the template could be applied to primary and secondary alcohols (Table 24, Entry 4).⁴⁸³ In general, site-selective C-H functionalization has become an efficient tool regarding the synthesis of complex molecules. Thereby, directing group assisted metallacycle formation serves as an efficient method to ensure promising regioselectivity, as demonstrated by a variety of *ortho*- and *meta*-C-H functionalizations. However, directing group assisted selective *para*-C-H functionalization in arenes has remained uninvestigated, because it includes the formation of a geometrically constrained metallacyclic transition state. Noteworthy, in 2015 Bag et al. reported an easily recyclable, novel Si-containing biphenyl-based template that directs efficient functionalization of the distal *p*-C-H bond of toluene by forming a D-shaped assembly. The complex template morphology enabled a large transition state that favored exquisite site selectivity in performing *para*-olefination and acetoxylation (Table 24, Entry 5).⁴⁸⁴

Table 24: Si- containing directing groups

Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
1		Alkenylation			Substrate (1 eq), acrylate (2 eq), [(RhCp*Cl2)2] (2.5 mol%) AgOTf (10 mol%), Cu(OAc)2 (1.2 equiv) in DCE at 60 °C for 24 h 19 examples, 21-90 % yield R ¹ : H, Me, OMe, halogenide R ² : Alkyl, aryl R ³ : Ester	480
2		Alkenylation			Substrate (0.3 mmol), alkene (0.6 mmol, 2 equiv), [Pd(OAc)2] (0.06 mmol, 20 mol%), AgOAc (0.6 mmol, 2 equiv), KH2PO4 (0.6 mmol, 2 equiv), CHCl3 (3.0 mL), 100 °C, 16 h. 25 examples, 36-91 % yield	481

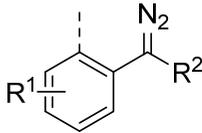
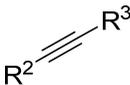
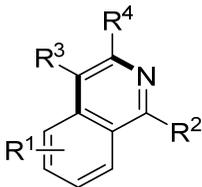
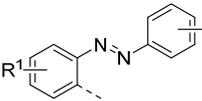
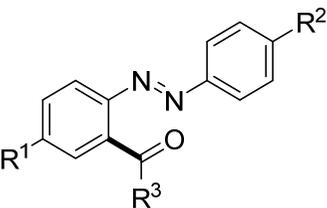
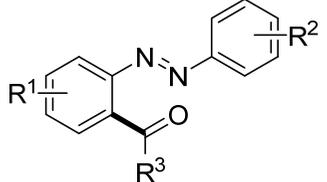
					<p>R¹: Me, OMe, halogenide, ester R²: H, Me R³: Ester, ketone, SO₂Me, CN, aryl, amide</p>	
3		Oxygenation	PhI(OAc) ₂		<p>Substrate (5 mmol), [Pd(OAc)₂] 5 mol%, PhI(OAc)₂ (1.2-1.5 equiv), PhCF₃ (0.1 M), 100°C 13 examples, 50-90 % yield R¹: Aryl, alkyl, <i>i</i>-Pr, naphthyl R²: H, aryl, alkyl</p>	482
4		Alkenylation			<p>Substrate (0.1 mmol), 1.5 equiv ethyl acrylate, Pd(OAc)₂ (10 mol%), Ac-Gly-OH (20 mol %), AgOAc (2 eq.), DCE, 90 °C, 24 h 18 examples, 8-84 % yield R¹, R²: Alkyl, <i>i</i>-Pr, <i>c</i>-Hx</p>	483
5		Acetoxylation	PhI(OAc) ₂		<p>Substrate (1 eq), Pd(OAc)₂ (15 mol%), Piv-Ala-OH (30 mol %), PhIOAc₂ (2 eq.); HFIP, 70 °C, 24 h 7 examples, 48-68 % yield R¹: Me, halogenide R²: H, Me</p>	484

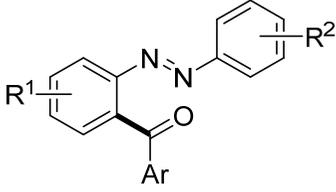
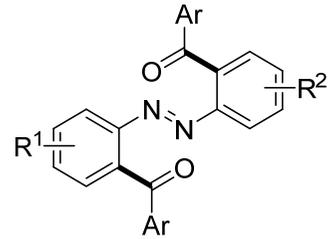
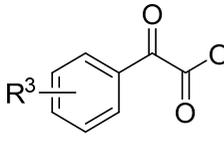
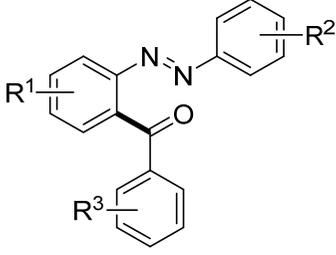
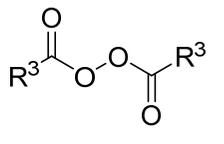
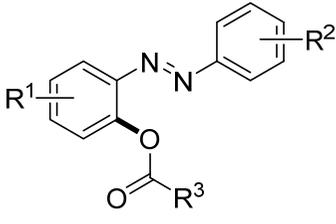
6		Alkenylation			<p>Substrate (1eq), 2 eq. alkene, Pd(OAc)₂ (10 mol%), Ac-Phe-OH (20 mol%), AgOAc (3 eq.); HFIP, 90 °C, 36 h</p> <p>27 examples, 48-76 % yield</p> <p>R¹: Me, OMe, halogenide, CF₃</p> <p>R²: H, Me, Ph</p> <p>R³, R⁴: H, ester, aryl</p>	484
7		Alkenylation			<p>Substrate (1 eq), alkene (4 equiv), Boc-Val-OH (20 mol %) as the ligand, 110 °C-120 °C, 24 h, 1 eq. Li₂CO₃, 4 eq. AgOAc, 10 mol% Pd(OAc)₂, traceless DG</p> <p>11 examples, 52-97 % yield</p> <p>R¹: Me, OMe, halogenide, OCF₃, alkyl</p>	485
8	 <p>n=1,2; m=1,2,3</p>	Alkylation		 <p>n=1,2; m=1,2,3</p>	<p>Substrate (0.2-0.4 mmol), diazo ester (1.1-4.0 eq), Rh₂OAc (2.5 mol%), DCM, RT</p> <p>7 examples, 62-95 % yield</p> <p>R¹, R²: Me, MePh</p> <p>R²: Alkyl</p>	479

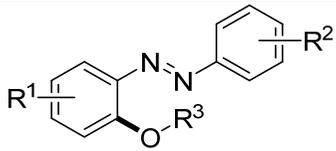
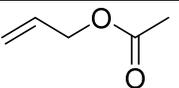
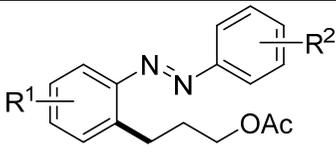
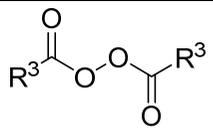
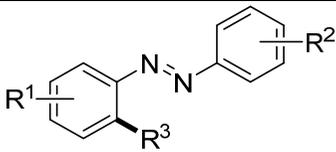
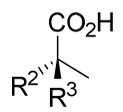
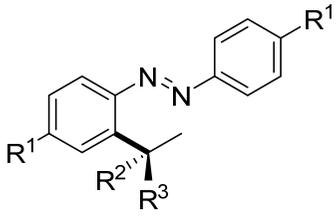
Azo-containing directing groups

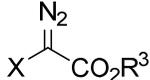
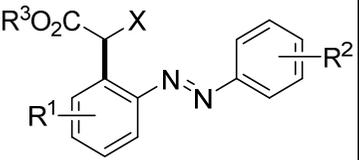
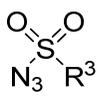
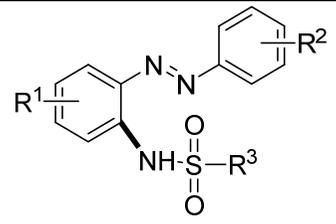
In 2013 the Wang group developed a Pd-catalyzed protocol for the synthesis of acylated azobenzenes from aromatic azo compounds and aldehydes via an azo-directed C-H bond activation process and with TBHP as an oxidant (Table 25, Entry 2).⁴⁸⁶ Moreover, an unprecedented C-H functionalization of aryl diazo compounds without a preinstallation of a directing group has been performed by Qiu et al. This procedure differs from other reports in its use of diazo compounds as coupling partners in directed C-H activations by application of a rhodium self-relay catalysis. This tandem process includes the in situ formation of a directing group and a sequential C-H bond activation (Table 25, Entry 1).⁴⁸⁷ Song et al. developed a protocol to synthesize *o*-acylazobenzenes through the Pd(II)-catalyzed C-H bond activation of azobenzenes with toluene derivatives, which are used as acylation reagent in this transformation. Further, diacylazobenzenes were obtained when TBHP loading was increased (Table 25, Entry 5).⁴⁸⁸ Moreover, an azo-group directed, highly regioselective synthesis of 2-alkoxy aromatic azo compounds via palladium(II)-catalyzed alkoxylation of azobenzene derivatives using alcohols as the alkoxylation reagents has been demonstrated by the Sum group. This method is applicable to both primary and secondary alcohols (Table 25, Entry 9).⁴⁸⁹ In 2015 Zhang et al. and Xia et al. reported a palladium catalyzed direct C-H bond sulfonylation of azobenzenes with arylsulfonyl chlorides (Table 25, Entry 22).^{490, 491} The first C-H aminocarbonylation of azoarenes with isocyanates by using rhenium catalysis was developed by Geng et al. This protocol provides a chemo- and regioselective approach to mono-C-H functionalized *o*-azobenzamides (Table 25, Entry 15).⁴⁹² The application of a rhodium-catalyst was reported for instance by Wang et al. A regioselective C-N bond formation of azo compounds through C-H bond functionalization using azides as the nitrogen source was developed. Alkyl, aryl, and sulfonyl azides were efficiently assembled in this reaction with excellent functional group tolerance (Table 25, Entry 16).⁴⁹³ Moreover, a rhodium(III)-catalyzed highly functional group-compatible synthesis of substituted indazoles is reported via C-H bond addition of azobenzenes to aldehydes. The regioselective coupling of unsymmetrical azobenzenes led to the development of a new removable aryl group that enables the preparation of indazoles without *N*-substitution by the Ellman group (Table 25, Entry 20).⁴⁹⁴ In 2014, a protocol for the Pd-catalyzed regioselective *ortho*-nitration of (*E*)-azoarenes has been reported for the first time using ^tBuONO as a nitrating agent under atmospheric oxygen (Table 25, Entry 21).⁴⁹⁵ In 2015 Premi et al. displayed a palladium catalyzed regioselective decarboxylative alkylation of (hetero)arenes with aliphatic carboxylic acids.⁴⁹⁶ Another cascaded procedure that also gives access to *ortho*-acyl azoarenes is the palladium catalyzed oxidation/ sp^2 C-H acylation of azoarenes with aryl methanes, which were used as in situ generated acyl sources (Table 25, Entry 1).⁴⁹⁷

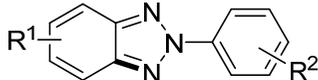
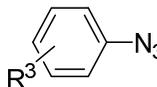
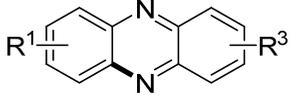
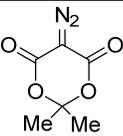
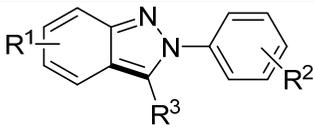
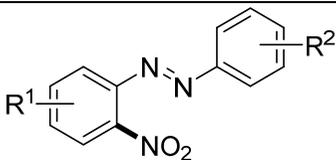
Table 25: Azo- containing directing groups

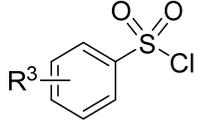
Entry	Directing group	Type of transformation	Coupling partner	Typical product structure	Comments	Ref
1		Cyclization			Substrate (0.2 mmol), alkyne (0.22 mmol), PhCO ₂ H (0.05 mmol), [Cp*RhCl ₂] ₂ (0.005 mmol), CH ₂ Cl ₂ (1 mL), MeOH (4 mL), 80 °C, 12 h 26 examples, 68-81 % yield R ¹ : Me, halogenide R ² : Aryl, alkyl R ³ : Aryl, alcohol R ⁴ : Aryl	487
2		Acylation			Substrate (0.20 mmol), aldehyde (0.22 mmol), Pd(OAc) ₂ (5.0 mol%), TBHP (0.40 mmol), DCE (1.0 mL), 80 °C, sealedtube, N ₂ , 12 h 24 examples, 54-85 % yield R ¹ , R ² : Me, halogenide, OMe R ³ : Alkyl, aryl, naphthyl, furane, cyclohexyl	486
3					Substrate (0.15 mmol), alcohol (1.0 equiv.) with Pd(OAc) ₂ (10 mol%) in the presence of TBHP (4.0 equiv.) in PhCl (2.0 mL) at 80 °C for 30 h under an argon atmosphere 30 examples, 20-80 % yield R ¹ , R ² : Me, OMe, halogenide, ester R ³ : Aryl, thiophenyl, alkyl	498

4			Ar-CH ₃		<p>Substrate (0.15mmol) and toluene (36.0 equiv) with Pd(OAc)₂ (10mol%) in the presence of TBHP (12.0 equiv) in PhCF₃ (1.0 mL) at 80 °C for 30 h under Ar in a sealed reaction tube; first step: oxidation of toluene</p> <p>34 examples, 15-79 % yield</p> <p>R¹, R²: Me, OMe, halogenide, ester, OCF₃</p>	497
5					<p>Substrate (0.2 mmol), toluene (1.5 mL), Pd(OAc)₂ (10 mol%), TBHP (4 equiv), CH₃CN (0.5 mL) at 80 °C</p> <p>Under air atmosphere for 24 h</p> <p>23 examples, 50-91 % yield</p> <p>R¹, R²: Me, OMe, halogenide, ester, OCF₃</p>	488
6			Ar-CH ₃		<p>Substrate (0.2 mmol), toluene derivatives (2 mL), Pd(OAc)₂ (10 mol%), TBHP (3 mmol) at 80 °C under air atmosphere for 24 h.</p> <p>10 examples, 53-83 % yield</p> <p>R¹, R²: Me, OMe, halogenide</p>	488
7					<p>Substrate (0.3 mmol), α-oxocarboxylicacids (0.33 mmol), Pd(OAc)₂ (10 mol%), K₂S₂O₈ (2 equiv), dioxane/AcOH/DMSO (7/2/1, 2 mL), 80 °C, 10 h</p> <p>23 examples, 50-88 % yield</p> <p>R¹, R²: Me, OMe, OEt, halogenide</p> <p>R³: Me, OMe, halogenide, CF₃, aryl</p>	499
8		Acyloxylation			<p>Substrate (0.15 mmol) and peroxides (2.0 equiv.) was stirred in the presence of Pd(OAc)₂ (10 mol%) in CH₃CN (2.0 mL) at 60 °C for 24 h under air conditions in a sealed tube. The ratio</p>	500

					of trans to cis diastereomers was determined by ^1H NMR spectroscopy 20 examples, 29-75 % yield R^1, R^2 : Me, OMe, halogenide, ester; R^3 : Aryl	
9	Alkoxylation	R^3OH		Substrate (0.5 mmol), alcohol (2 mL), $\text{Pd}(\text{OAc})_2$ (10 mol%), and $\text{PhI}(\text{OAc})_2$ (1.0 mmol) under an air atmosphere at 80 °C for 24 h 24 examples, 35-77 % yield R^1, R^2 : Me, OMe, halogenide, ketone, ester; R^3 : Alkyl	489	
10	Alkylation			Substrate (0.40 mmol), allyl acetate (0.30 mmol), $[\text{Cp}^*\text{RhCl}_2]_2$ (3 mol%), AgSbF_6 (15 mol%), DCE (1.0 mL) at 110 °C in air for 20 h 25 examples, 52-80 % yield R^1, R^2 : Me, OMe, halogenide, CF_3 , <i>i</i> -Pr	501	
11				Substrate (0.15 mmol) and peroxides (2.0 equiv.) was stirred at 130 °C in the presence of $\text{Pd}(\text{OAc})_2$ (10 mol%) in PhCl (2.0 mL) for 24 h under air conditions in a sealed tube. The ratio of trans to cis diastereomers was determined by ^1H NMR spectroscopy 18 examples, 23-82 % yield R^1, R^2 : Me, OMe, halogenide, ester R^3 : Aryl	500	
12				Substrate (1.0 equiv), carboxylic acid (2.0 equiv), $\text{PhI}(\text{OAc})_2$ (2.0equiv), $\text{Pd}(\text{OAc})_2$ (10 mol%), 80 °C, 2 h 24 examples, 12-77 % yield R^1 : Me, halogenide R^2, R^3 : Alkyl	496	

13					<p>Substrate (0.2 mmol), RhCp*Cl₂]₂ (2.5 mol %), AgSbF₆ (10 mol%), THF (1 mL) under air at 60 °C for 20 h</p> <p>20 examples, 23-89 % yield</p> <p>R¹, R²: Me, OMe, halogenide, OCF₃, ester</p> <p>R³: Alkyl, aryl, <i>i</i>-Pr</p> <p>X: CO₂R, SO₂Ph, PO(OEt)₂, CPh</p>	502
14		Amidation			<p>Substrate (1.5 eq.), [Cp*RhCl₂]₂ (5 mol%); sulfonylazide (1 eq.), AgNTf₂ (20 mol%); 1,2-dichloroethane; 90 °C; 36 h</p> <p>23 examples, 35-98 % yield</p> <p>R¹, R²: Me, OMe, halogenide, OCF₃, NO₂</p> <p>R³: Alkyl, aryl, thiophenyl, naphthyl</p>	503
15		Amidation			<p>Substrate (1.25 mmol), isocyanate (0.5 mmol), Re₂(CO)₁₀ (0.025 mmol), NaOAc (0.1 mmol), toluene (2.5 mL), 130 °C, 24 h</p> <p>30 examples, 42-86 % yield</p> <p>R¹, R²: Me, OMe, OCF₃, OCF₃, halogenide, aryl</p> <p>R³: Alkyl, aryl, naphthyl</p>	492
16		Amination	R ³ -N ₃		<p>Substrate (0.5 mmol), [RhCp*Cl₂]₂ (2.5 mol%), RN₃ (1.5 eq.); AgSbF₆ (10 mol%); DCE; under air; 85 °C; 36-40 h; alkyl, aryl, and sulfonylazides could be efficiently assembled in this reaction.</p> <p>35 examples, 46-97 % yield</p> <p>R¹, R²: Me, OMe, acetyl, halogenide, ester</p> <p>R³: Aryl, alkyl, sulfonyl</p>	493

17			TMSN ₃		Substrate (0.5 mmol), Pd(OAc) ₂ , TMSN ₃ (2 equiv), TBHP-decane (2 equiv) in DMSO (1.0 mL) at 100 °C for 19–50 h 18 examples, 8-87 % yield R ¹ , R ² : H, Me, OMe, alkyl, halogenide, CF ₃	504
18					Substrate (0.2 mmol), azide (0.3 mmol), [RhCp*Cl ₂] ₂ (5 mol%); AgB(C ₆ F ₅) ₄ (20 mol %); AcOH; 110 °C; 24 h 10 examples, 30-88 % yield R ¹ : Me, halogenide, acetyl, CF ₃ ; R ² : Me; R ³ : Me, acetyl, halogenide, CF ₃	505
19					Substrate (0.2 mmol), diazo derivative of Meldrum's Acid (0.3 mmol), [RhCp*Cl ₂] ₂ (2.5 mol%), AgSbF ₆ (10 mol %), MeOH (1 mL), under air at 80 °C for 8 h 7 examples, 30-89 % yield R ¹ , R ² : Me, halogenide	502
20			R ³ CHO		Substrate (0.20 mmol), aldehyde (0.40 mmol), [Cp*RhCl ₂] ₂ (5 mol%), AgSbF ₆ , 100mg of MgSO ₄ in 1.0 mL of THF, 110 °C, 24 h 22 examples, 38-81 % yield R ¹ , R ² : Me, halogenide, OH, amide, CF ₃ R ³ : Aryl	494
21		Nitration	^t BuONO		Substrate (0.5 mmol), ^t BuONO (2.0 mmol), Pd(CH ₃ CN) ₂ Cl ₂ (15 mol%), 1,4-dioxane (3 mL), 90 °C, 20 h, under air 19 examples, 40-92 % yield R ¹ , R ² : Alkyl, NO ₂ , halogenide, CF ₃	495

22		Sulfonylation			<p>Substrate (0.5 mmol), arylsulfonyl chlorides (0.6 equiv.), catalyst (10 mol%), base (2.0 equiv.), 4A MS (100 mg) and solvent (2.0 mL) under air at 130 °C for 12 h</p> <p>21 examples, 15-92 % yield</p> <p>R¹, R²: Me, OMe, OEt, halogenide</p> <p>R³: Me, OMe, alkyl, halogenide, NO₂</p>	490
23					<p>Substrate (0.2 mmol), arylsulfonyl chlorides (3.0 equiv), Pd(TFA)₂ (5 mol %), and K₂S₂O₈ (1.1 equiv) in DCE (2.0 mL) under air at 120 °C for 36 h</p> <p>28 examples, 20-92 % yield</p> <p>R¹, R²: Me, OMe, OCF₃, halogenide, ester</p> <p>R³: H, Me, OMe, alkyl, halogenide, CN, CF₃</p>	491

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